

2024년 1월 25일(목), 09:00-10:45 Room A(101),1층

#### L. Analog Design 분과

[TA1-L] Analog Circuits

#### 좌장: 엄지용 교수(금오공과대학교), 정영호 교수(대구대학교)

초청발표 TA1-L-1 09:00-09:30	2전극 측정을 위한 저 잡음 넓은 동적영역의 바이오 임피던스 판독회로 손현우 경상국립대학교
TA1-L-2 09:30-09:45	A Fully Differential LiDAR Receiver with On-chip APDs in 180-nm CMOS Yejin Choi <sup>1,2</sup> , Yunji Song <sup>1,2</sup> , Juntong Li <sup>1,2</sup> , Yeojin Chon <sup>1,2</sup> , Shinhae Choi <sup>1,2</sup> , Xinyue Zhang <sup>1,2</sup> , and Sung Min Park <sup>1,2</sup> <sup>1</sup> Depatment of Electronic and Electrical Engineering, Ewha Womans University, <sup>2</sup> Graudate Program in Smart Factory, Ewha Womans University
TA1-L-3 09:45-10:00	An 8x8 Optoelectronic Receiver Array in 180-nm CMOS for Elder-Care Short Range LiDAR Sensors Shinhae Choi <sup>1,2</sup> , Yeojin Chon <sup>1,2</sup> , Yunji Song <sup>1,2</sup> , Yejin Choi <sup>1,2</sup> , and Sung Min Park <sup>1,2</sup> <sup>1</sup> Depatment of Electronic and Electrical Engineering, Ewha Womans University, <sup>2</sup> Graudate Program in Smart Factory, Ewha Womans University
TA1-L-4 10:00-10:15	A Fully-Differential Optoelectronic Receiver in 180-nm CMOS Yunji Song <sup>1,2</sup> , Yejin Choi <sup>1,2</sup> , Juntong Li <sup>1,2</sup> , Shinhae Choi <sup>1,2</sup> , Yeojin Chon <sup>1,2</sup> , Xinyue Zhang <sup>1,2</sup> , and Sung Min Park <sup>1,2</sup> <sup>1</sup> Depatment of Electronic and Electrical Engineering, Ewha Womans University, <sup>2</sup> Graudate Program in Smart Factory, Ewha Womans University
TA1-L-5 10:15-10:30	Single-stage Wireless CC-CV Resonant Battery Charger with Coupling Range Extension Scheme for Implantable Biomedical Applications Byeong Woo Yoo, Joon Gyu Kim, Min Jae Kim, Min Sung Kim, and Sung Yun Park Pusan National University
TA1-L-6 10:30-10:45	A 2nd Order Delta-sigma Modulator for BMS DC Measurement Ji-Ho Park, Jae-Geun Lim, Hyoung-Jung Kim, Jae-Hyuk Lee, Seong-Bo Park, Byeong-Ho Yu, and Gil Cho Ahn Department of Electronic Engineering, Sogang University

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 25일(목), 09:00-10:45 Room B(102),1층

#### H. Display and Imaging Technologies 분과

#### [TB1-H] Display and Imaging Technologies I

#### 좌장: 정윤영 교수(POSTECH), 진성훈 교수(인천대학교)

	·····
++1417	Hybrid-Multiscale Materials Enabled Light-to-Frequency-Conversion
초청발표	Circuits Toward IoT Security Application
TB1-H-1	Sung Hun Jin, Seung Gi Seo, Mokurala Krishnaiah, and Dhananjay Mishra
09:00-09:30	I-Nanofab Center, Department of Electronic Engineering, Incheon National
	University
	Effects of ZnMgO Surface UV Treatment on the Performance of InP-
TB1-H-2	Based Inverted Quantum Dot Light-Emitting Diodes
	Hyeong Jin Kim <sup>1,2</sup> and Jeonghun Kwak <sup>1,2</sup>
09:30-09:45	<sup>1</sup> Department of Electrical and Computer Engineering, Seoul National University,
	<sup>2</sup> ISRC, Seoul National University
	Strategy for High Quantum-efficient AlGaInP/GaInP Micro-red LEDs
	and The Demonstration of 1700 PPI Ultra-high-resolution Mono-color
	Display through Monolithic 3D Integration Technology
TB1-H-3	Juhyuk Park <sup>1</sup> , Dae-Myeong Geum <sup>2</sup> , Dong-Soon Jung <sup>3</sup> , Woojin Baek <sup>1</sup> , Hyunsu
09:45-10:00	Kim <sup>1</sup> , and Sanghyeon Kim <sup>1</sup>
	<sup>1</sup> Electrical Engineering, KAIST, <sup>2</sup> School of Electronics Engineering, Chungbuk
	National University, <sup>3</sup> RAONTECH Inc.
	Solution-Processed NIR Sensing Ambipolar Organic Phototransistor
TB1-H-4	HwaPyeong Noh, Yongju Lee, MiRiNae Lee, Hyo Won Jang, Swarup Biswas, and
10:00-10:15	Hyeok Kim
10.00-10.13	School of Electrical and Computer Engineering, University of Seoul
	Vertically Stacked RGB Micro-LEDs Via Transfer Printed
TB1-H-5	Semiconductor Sheets
10:15-10:30	Seong Woo Hong and Yei Hwan Jung
	Department of Electronic Engineering, Hanyang University
	Quantum Efficiency Enhancement by Using Guided-Mode Resonance
TB1-H-6 10:30-10:45	Structure on eSWIR T2SL nBn Photodetector
	Dongho Gwak, Seung-Yeop Ahn, Jinha Lim, and Sang Hyeon Kim
10.00 10.40	School of Electrical Engineering, KAIST
	pochosi or Electrical Engineering, Malor



2024년 1월 25일(목), 09:00-10:45 Room C(103),1층

J. Nano-Science & Technology 분과

[TC1-J] van der Waals Heterostructure Electronics

좌장: 이관형 교수(서울대학교), 이명재 교수(서울대학교)

초청발표 TC1-J-1 09:00-09:30	2D Materials Design for Angstrom-scale Multi-stack Devices Hyeon-Jin Shin SAIT
TC1-J-2 09:30-09:45	NMOS Inverter based on Vertically Stacked MoS <sub>2</sub> n-MOSFET Using Semi-metallic PtSe <sub>2</sub> Contacts Jae Eun Seo <sup>1</sup> , Minseung Gyeon <sup>2</sup> , Jisoo Seok <sup>1</sup> , Kibum Kang <sup>2</sup> , and Jiwon Chang <sup>1</sup> <sup>1</sup> Department of System Semiconductor Engineering and Department of Materials Science and Engineering, Yonsei University, <sup>2</sup> Department of Materials Science and Engineering, KAIST
TC1-J-3 09:45-10:00	Atomic-Thin Dielectric Integration with Hexagonal Boron Nitride for Large Scale MoS <sub>2</sub> Field Effect Transistors Woo-Ju Lee <sup>1,2</sup> , Min-Yeong Choi <sup>1,2</sup> , Seong-Jun Yang <sup>1</sup> , and Cheol-Joo Kim <sup>1,2</sup> <sup>1</sup> Center for Van der Waals Quantum Solids, IBS, <sup>2</sup> Department of Chemical Engineering, POSTECH
초청발표 TC1-J-4 10:00-10:30	Reliable Transistors Fabricated via Two-dimensional Layer Transfer Assisted Heterogeneous Integration Techniques Hyun S. Kum Yonsei University
TC1-J-5 10:30-10:45	Two-dimensional Layer Induced Resistive Switching Properties of Hafnia-Based Heterostructure Donghyeon Lee <sup>1</sup> , Seungmo Kim <sup>2,3</sup> , and Sanghan Lee <sup>1</sup> <sup>1</sup> School of Materials Science and Engineering, GIST, <sup>2</sup> Center for Semiconductor Technology Convergence, POSTECH, <sup>3</sup> Department of Electrical Engineering, POSTECH



2024년 1월 25일(목), 09:00-10:45 Room D(104),1층

P. Device for Energy (Solar Cell, Power Device, Battery, etc.) 분과 [TD1-P] 태양광 / 파워 디바이스

#### 좌장: 유상우 교수(경기대학교), 박정웅 교수(가천대학교)

TD1-P-1 09:00-09:15	Chip Size Dependent Turn-off Behavior of SiC MOSFETs
	Yeonjun Kim and Hyemin Kang
	Department of Energy Engineering, KENTECH
	Microstructure Design of n-type Bi <sub>2</sub> Te <sub>3</sub> Alloys via Selective Dissolution
	of KCI: Influence of Bi2TeO5 Formation over an Eutectic Point
TD1-P-2	Gwang Min Park <sup>1,2</sup> , Seunghyeok Lee <sup>2,3</sup> , Jun-Yun Kang <sup>4</sup> , Seung-Hyub Baek <sup>2</sup> ,
09:15-09:30	Heesuk Kim <sup>1</sup> , Jin-Sang Kim <sup>1</sup> , and Seong Keun Kim <sup>1,2</sup>
	<sup>1</sup> KU-KIST, Korea University, <sup>2</sup> KIST, <sup>3</sup> Hanyang University, <sup>4</sup> Korea Institute of Materials
	Science
	$MoS_{2(1\text{-}x)}Te_{2x}$ / $MoS_2$ Van Der Waals Heterojunctions for Ultra-Thin
TD1-P-3	Photovoltaic Application
09:30-09:45	Dong Hyun Seo <sup>1,2</sup> , Guen Hyung Oh <sup>1,2</sup> , Jong Min Song <sup>1,2</sup> , and TaeWan Kim <sup>1,2</sup>
09.30-09.45	<sup>1</sup> Department of Electrical Engineering, Jeonbuk National University, <sup>2</sup> Smart Grid
	Research Center, Jeonbuk National University
초청발표	Efficient Stable and Scalable Derevel/ite Scler Calls
	Efficient, Stable and Scalable Perovskite Solar Cells
TD1-P-4	Jangwon Seo
09:45-10:15	Department of Chemical & Biomolecular Engineering, KAIST
	산화갈륨 기반 수직형 고전압 쇼트키 다이오드 구조 설계를 위한 해석적 모
TD1-P-5	델 제안
	Min-Jeoung Kim, Sung-Hoon Lee, Won-Chul Chol, Seung-Jun Oh, Ji-Ho Kim, and
10:15-10:30	Ho-Young Cha
	School of Electronic and Electrical Engineering, Hongik University
	ALD BeO Grown on (-201) and (001) $\beta\text{-}\text{Ga}_2\text{O}_3$ Substrates for Power
TD1-P-6 10:30-10:45	Devices
	Dohwan Jung <sup>1</sup> , Yoonseo Jang <sup>1</sup> , Sangoh Han <sup>1</sup> , Christopher W. Bielawski <sup>2</sup> and
	Jungwoo Oh <sup>1</sup>
	<sup>1</sup> School of Integrated Technology, Yonsei University, <sup>2</sup> CMCM, IBS, Department of
	Chemistry, UNIST

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 25일(목), 09:00-10:45 Room E(105),1층

#### E. Compound Semiconductors 분과

[TE1-E] Compound Semiconductor - InP Electronic Devices

좌장: 이기원 교수(원광대학교)

초청발표 TE1-E-1	InP HEMT Based MMICs for Future Quantum Computing Applications Sang-jin Yoon <sup>1</sup> , Sang-kuk Kim <sup>1</sup> , Ted Kim <sup>1</sup> , and Dae-hyun Kim <sup>2</sup>
09:00-09:30	<sup>1</sup> QSI, <sup>2</sup> School of Electronic and Electrical Engineering, Kyungpook National University
TE1-E-2 09:30-09-45	$ \begin{array}{l} L_g = 60 \ nm \ 5\text{-levels-stacked } In_{0.53}Ga_{0.47}As \ MBCFETs \ with \ Q = 258 \\ \text{JH. Yoo}^1, \ \text{HB. Jo}^{1,2}, \ \text{IG. Lee}^1, \ \text{SM. Choi}^1, \ \text{HJ. Kim}^1, \ \text{WS. Park}^1, \ \text{H. Jang}^3, \\ \text{CS. Shin}^3, \ \text{KS. Seo}^3, \ \text{S. H. Shin}^4, \ \text{HM. Kwon}^4, \ \text{SK. Kim}^5, \ \text{JG. Kim}^5, \ \text{J. Yun}^5, \ \text{T. Kim}^5, \ \text{JH. Lee}^1, \ \text{and } \ \text{DH. Kim}^1 \\ \ ^1\text{Kyungpook National University, } ^2\text{KETI, } ^3\text{KANC, } ^4\text{Polytech, } ^5\text{QSI} \end{array} $
TE1-E-3 09:45-10:00	Cryogenic InGaAs HEMTs with Nb Superconductor for RF Transistors and Routing Circuits in Quantum Computing Jaeyong Jeong <sup>1</sup> , Seong Kwang Kim <sup>1</sup> , Yoon-Je Suh <sup>1</sup> , Nahyun Rheem <sup>1</sup> , Jisung Lee <sup>2</sup> , Joonyoung Choi <sup>3</sup> , Juhyuk Park <sup>1</sup> , Joon Pyo Kim <sup>1</sup> , Bong Ho Kim <sup>1</sup> , Younjung Jo <sup>3</sup> , Seung-Young Park <sup>2</sup> , Jongmin Kim <sup>4</sup> , and Sanghyeon Kim <sup>1</sup> <sup>1</sup> School of Electrical Engineering, KAIST, <sup>2</sup> Center for Scientific Instrumentation, KBSI, <sup>3</sup> Department of Physics, Kyungpook National University, <sup>4</sup> KANC
TE1-E-4 10:00-10:15	Experimental Investigation of Scattering Mechanism in In <sub>0.8</sub> Ga <sub>0.2</sub> As HEMTs at Cryogenic Temperature Seung-Woo Son <sup>1</sup> , Ji-Hoon Yoo <sup>1</sup> , Min-Seo Yu <sup>1</sup> , Wan-Soo Park <sup>1</sup> , In-Geun Lee <sup>1</sup> , Jae- Hak Lee <sup>1</sup> , Kyounghoon Yang <sup>2</sup> , and Dae-Hyun Kim <sup>1</sup> <sup>1</sup> School of Electronic and Electrical Engineering, Kyungpook National University, <sup>2</sup> KAIST
TE1-E-5 10:15-10:30	A Simple Yet Physical Model for Cutoff Frequency and Maximum Oscillation Frequency of High-electron-mobility Transistors In-Geun Lee <sup>1</sup> , Su-Min Choi <sup>1</sup> , Hyeon-Bhin Jo <sup>1,2</sup> , Wan-Soo Park <sup>1</sup> , Ji-Hoon Yoo <sup>1</sup> , Hyo- Jin Kim <sup>1</sup> , Takuya Tsutsumi <sup>3</sup> , Hiroki Sugiyama <sup>3</sup> , Hideaki Matsuzaki <sup>3</sup> , Jae-Hak Lee <sup>1</sup> , and Dae-Hyun Kim <sup>1</sup> <sup>1</sup> Kyungpook National University, <sup>2</sup> KETI, <sup>3</sup> NTT Device Technology Laboratories
TE1-E-6 10:15-10:45	Improved Thermal Reliability in Base Contact of Full 3-inch InP Double-HBTs with $f_T$ and $f_{max}$ in Excess of 300 GHz Yong-Soo Jeon <sup>1</sup> , In-Geun Lee <sup>1</sup> , Yonghyun Kim <sup>2</sup> , Jacob Yun <sup>2</sup> , Ted Kim <sup>2</sup> , Hyuk-Min Kwon <sup>3</sup> , Seung Heon Shin <sup>3</sup> , Jae-Hak Lee <sup>1</sup> , Kyounghoon Yang <sup>4</sup> , and Dae-Hyun Kim <sup>1</sup> <sup>1</sup> Kyungpook National University, <sup>2</sup> QSI, <sup>3</sup> Korea Polytechnics, <sup>4</sup> KAIST

### 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 25일(목), 09:00-10:45 Room F(106),1층

C. Material Growth & Characterization 분과

[TF1-C] Advanced Characterization of 2D Materials

좌장: 윤석준 교수(울산대학교), 이승훈 교수(부경대학교)

초청발표 TF1-C-1 09:00-09:30	Operando Electron Microscopy Investigation of Domain Dynamics in 2D Sliding Ferroelectrics Hyobin Yoo Sogang University
TF1-C-2 09:30-09:45	Graphene Capping Layer in Cu Back-End-Of-Line Keun Wook Shin, Yeonchoo Cho, and Kyung-Eun Byun SAIT
TF1-C-3 09:45-10:00	Modulating Polymorph Transition Metal Dichalcogenides through Controlled Thermal and Plasma Treatments Dongho Lee <sup>1</sup> , Hyunho Seok <sup>2</sup> , Sihoon Son <sup>2</sup> , Hyunbin Choi <sup>3</sup> , Gunhyoung Kim <sup>3</sup> , and Taesung Kim <sup>1,2,3</sup> <sup>1</sup> Department of Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> SAINT, Sungkyunkwan University, <sup>3</sup> Department of Semiconductor Convergence Engineering, Sungkyunkwan University
초청발표 TF1-C-4 10:00-10:30	Facile and Large-area Optical Characterization of Atomically Thin Films Jae-Ung Lee Ajou University
TF1-C-5 10:30-10:45	Thermal Property 3D Imaging System Using Frequency-domain Thermoreflectance Jihyun Kim, Jongwon Baek, and Jungwan Cho Sungkyunkwan University



2024년 1월 25일(목), 09:00-10:45 Room G(201),2층

### K. Memory (Design & Process Technology) 분과

#### [TG1-K] RRAM and Neuromorphic Device I

#### 좌장: 김수길 팀장(SK하이닉스), 권건우 교수(홍익대학교)

TG1-K-1 09:00-09:15	CMOS-compatible, 2DEG-Based Three-terminal Dynamic Memristor Woon Hyung Cheong, Geunyoung Kim, and Kyung Min Kim KAIST
TG1-K-2 09:15-09:30	A Memristor-Based Elementary Motion Detector for a Maneuver Prediction Min Gu Lee, Hanchan Song, Gwangmin Kim, Kyung Min Kim Department of Materials Science and Engineering, KAIST
TG1-K-3 09:30-09:45	Reconfigurable Two-dimensional Tellurene Artificial Synapse for Bio- inspired Wearable Edge Computing Bolim You <sup>1</sup> , Jeechan Yoon <sup>1</sup> , Yuna Kim <sup>1</sup> , Mino Yang <sup>2</sup> , Jina Bak <sup>1</sup> , Jihyang Park <sup>1</sup> , Jihoon Huh <sup>1</sup> , Myung Gwan Hahm <sup>1</sup> , and Moonsang Lee <sup>1</sup> <sup>1</sup> Inha University, <sup>2</sup> Korea Basic Science Institute Seoul
TG1-K-4 09:45-10:00	Strategy to Improve Synaptic Behavior of Ion-actuated Synaptic Transistors – the Use of Ion Blocking Layer for Reliable Multilevel Retention Seonuk Jeon <sup>1</sup> , Nayeon Kim <sup>1</sup> , Eunryeong Hong <sup>1</sup> , Hyun Wook Kim <sup>1</sup> , Yunsur Kim <sup>2</sup> , Hyeonsik Choi <sup>2</sup> , Hyoungjin Park <sup>2</sup> , Jiae Jeong <sup>2</sup> , and Jiyong Woo <sup>1,2</sup> <sup>1</sup> School of Electronic and Electrical Engineering, Kyungpook National University, <sup>2</sup> School of Electronics Engineering, Kyungpook National University
TG1-K-5 10:00-10:15	Role of Oxide Barrier in a NbO <sub>x</sub> Layer with Noninert Electrodes for High-yield Threshold Switching Characteristics Hyeonsik Choi <sup>1</sup> , Hyun Wook Kim <sup>2</sup> , Eunryeong Hong <sup>2</sup> , Nayeon Kim <sup>2</sup> , Seonuk Jeon <sup>2</sup> , Yunsur Kim <sup>1</sup> , Hyoungjin Park <sup>1</sup> , Jiae Jeong <sup>1</sup> , and Jiyong Woo <sup>1,2</sup> <sup>1</sup> School of Electronic Engineering, Kyungpook National University, <sup>2</sup> School of Electronic and Electrical Engineering, Kyungpook National University

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TG1-K-6 10:15-10:30	A 10T2R Non-Volatile SRAM Cell Design with High-Reliability So Yeon Kwon, Woon San Ko, Jun Ho Byun, Do Yeon Lee, and Ga Won Lee Chungnam National University
TG1-K-7 10:30-10:45	Impact of Al <sub>2</sub> O <sub>3</sub> Layer on Nonlinearity of Selector-less HfO <sub>x</sub> -Based RRAM for Neuromorphic Computing Applications Yunsur Kim <sup>1</sup> , Hyun Wook Kim <sup>2</sup> , Eunryeong Hong <sup>2</sup> , Nayeon Kim <sup>2</sup> , Seonuk Jeon <sup>2</sup> , Hyeonsik Choi <sup>1</sup> , Hyoungjin Park <sup>1</sup> , Jiae Jeong <sup>1</sup> , and Jiyong Woo <sup>1,2</sup>
	<sup>1</sup> School of Electronic Engineering, Kyungpook National University, <sup>2</sup> School of Electronic and Electrical Engineering, Kyungpook National University

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2024년 1월 25일(목), 09:00-10:45 Room H(202),2층

#### K. Memory (Design & Process Technology) 분과

[TH1-K] Processing In Memory

좌장: 구민석 교수(인천대학교)

초청발표 TH1-K-1 09:00-09:30	A Fully Integrated Hybrid Memristor–CMOS System for Efficient Vector-Matrix Multiplication Operations Seung Hwan Lee Kyung Hee University
ТН1-К-2 09:30-09:45	Compact and High-performance 4T Ternary Content-addressable Memory Utilizing Dual-gate Metal Oxide Transistors Taewon Seo <sup>1</sup> , Seongmin Park <sup>1</sup> , and Yoonyoung Chung <sup>1,2,3</sup> <sup>1</sup> Department of Electrical Engineering, POSTECH, <sup>2</sup> Department of Semiconductor Engineering, POSTECH, <sup>3</sup> Center for Semiconductor Technology Convergence, POSTECH
TH1-K-3 09:30-09:45	Device-algorithm Co-optimization for an On-chip Trainable Capacitor Based Synaptic Device with IGZO TFT and Retention-centric Tiki-Taka Algorithm Jaehyeon Kang <sup>1</sup> , Jongun Won <sup>1</sup> , Narae Han <sup>1</sup> , Minseung Kang <sup>1</sup> , Yeaji Park <sup>1</sup> , Youngchae Roh <sup>1</sup> , Hyeongjun Seo <sup>1</sup> , Changhoon Joe <sup>1</sup> , Ung Cho <sup>1</sup> , Minil Kang <sup>2</sup> , Minseong Um <sup>2</sup> , Hyung-Min Lee <sup>2</sup> , Saeroonter Oh <sup>3</sup> , and Sangbum Kim <sup>1</sup> <sup>1</sup> Seoul National University, <sup>2</sup> Korea University, <sup>3</sup> Hanyang University
ТН1-К-4 09:45-10:00	Highly Accurate Multi-bit Multiplier Composed of IGZO 2TOC Unit Cells Taejun Ha <sup>1</sup> , Suwon Seong <sup>1</sup> , Seongmin Park <sup>1</sup> , Hyunyoung Cho <sup>1</sup> , and Yoonyoung Chung <sup>1,2,3</sup> <sup>1</sup> Department of Electrical Engineering, <sup>2</sup> Department of Semiconductor Engineering, <sup>3</sup> Center for Semiconductor Technology Convergence, POSTECH
ТН1-К-5 10:00-10:15	A Heater-embodying Rapid and Energy-efficient Mott True Random Number Generator Array for Secure Communication Gwangmin Kim, Jae Hyun In, and Kyung Min Kim Department of Materials Science and Engineering, KAIST



2024년 1월 25일(목), 09:00-10:45 Room I(203),2층

#### D. Thin Film Process Technology 분과

[TI1-D] Emerging Devices

#### 좌장: 윤성민 교수(경희대학교), 이웅규 교수(숭실대학교)

TI1-D-1 09:00-09:15	Oxide Based Synaptic Transistors Implementing Multi-valued Logic Function Jung Wook Lim <sup>1,2</sup> and Min A Park <sup>1</sup> <sup>1</sup> ETRI, <sup>2</sup> University of Science and Technology
TI1-D-2 09:15-09:30	Study on Threshold Switching Behavior of Oxide Thin Film Based Devices; a New Type of Selector Ju Hwan Park <sup>1</sup> , Ji Young Park <sup>1</sup> , Hye Rim Kim <sup>2</sup> , Tae Jung Ha <sup>3</sup> , Jeong Hwan Song <sup>3</sup> , Soo Gil Kim <sup>3</sup> , Tae Joo Park <sup>2</sup> , and Byung Joon Choi <sup>1</sup> <sup>1</sup> Seoul National University of Science and Technology, <sup>2</sup> Hanyang University, <sup>3</sup> SK hynix
TI1-D-3 09:30-09:45	Energy Efficient Electrolytic-gated Synapse Transistors Using InGaZnO/HfO2 Gate Stacks with Vertical Channel Configurations Dong-Hee Kim <sup>1</sup> , Young-Ha Kwon <sup>2</sup> , Nak-Jin Seong <sup>2</sup> , Kyu-Jeong Choi <sup>2</sup> , Jong-Heon Yang <sup>3</sup> , Chi-Sun Hwang <sup>3</sup> , and Sung-Min Yoon <sup>1</sup> <sup>1</sup> Kyung Hee University, <sup>2</sup> NCD Co., Ltd., <sup>3</sup> ETRI
TI1-D-5 09:45-10:00	Self-Rectifying Resistive Switching Device for 1k Crossbar Array Structure Hyun Kyu Seo, Su Yeon Lee, Se Yeon Jeong, June hyuk Lee, Min Kyung Lee, and Min Kyu Yang Intelligent Electronic Device Lab, Sahmyook University
초청발표 TI1-D-6 10:00-10:30	Atomic Layer Deposition Approaches for High- Resolution/Performance Collidal Quantum Dot Display Applications Seong-Yong Cho, Joon Yup Lee, and Eun A Kim Department of Photonics and Nanoelectronics, Hanyang University ERICA



2024년 1월 25일(목), 09:00-10:45 Room J(204),2층

A. Interconnect & Package 분과

[TJ1-A] Emerging Interconnect

좌장: 김병준 교수(한국공학대학교), 주지호 박사(한국전자통신연구원)

TJ1-A-1 09:00-09:15	나노 초 레이저 어닐링을 이용한 비아 플러그의 결정립 크기 증가 정재중 <sup>1</sup> , 박영근 <sup>1</sup> , 백용구 <sup>1</sup> , 김희태 <sup>1</sup> , 김동빈 <sup>1</sup> , 김환욱 <sup>2</sup> , 조병진 <sup>1</sup> <sup>1</sup> 한국과학기술원 전기 및 전자공학부, <sup>2</sup> 한국기초과학지원연구원 소재분석연구부
TJ1-A-2 09:15-09:30	Atomic Layer Deposition of RuO <sub>2</sub> for a Diffusion Barrier in Ru- interconnects Minsu Kim <sup>1</sup> , Youn-Hye Kim <sup>2</sup> , Ki-Seok An <sup>3</sup> , and Soo-Hyun Kim <sup>4</sup> <sup>1</sup> Kyonggi University, <sup>2</sup> Yeungnam University, <sup>3</sup> KRICT, <sup>4</sup> UNIST
TJ1-A-3 09:30-09:45	Electromigration Reliability of Barrierless Ruthenium and Molybdenum for Sub-10 nm Interconnection Jungkyun Kim, Hakseung Rhee, and Kyung Min Kim KAIST
TJ1-A-4 09:45-10:00	Reduced Size Effect of Resistivity in Cobalt-Palladium (CoPd) Alloys for Advanced Interconnection Applications Hyeong Jun Kim <sup>1</sup> , Kiyoung Lee <sup>2</sup> , Tae Won Jeong <sup>3</sup> , Keon Wook Shin <sup>3</sup> , Sang Won Kim <sup>3</sup> , and Changhwan Choi <sup>1</sup> <sup>1</sup> Division of Materials Science and Engineering, Hanyang University, <sup>2</sup> Department of Materials Science and Engineering, Hongik University, <sup>3</sup> SAIT
TJ1-A-5 10:00-10:15	Selective Deposition of ALD Barrier Metal for Extremely Advanced Cu Interconnect 김기현, 장준기, 박경필, 박치범, 박은영, 이재호, 정은지, 박두환, 김진, 김락환, 하태 홍, 안정훈, 이종호 Foundry business, Samsung Electronics Co., Ltd.
초청발표 TJ1-A-6 10:15-10:45	Improving Mechanical-electrical Reliability of Cu Interconnects based on the Microstructure Analysis Seongi Lee <sup>1</sup> , Jun Hyeok Hyun <sup>2</sup> , and So-Yeon Lee <sup>2</sup> <sup>1</sup> Seoul National University, <sup>2</sup> Kumoh National Institute of Technology



2024년 1월 25일(목), 09:00-10:45 Room K(205),2층

G. Device & Process Modeling, Simulation and Reliability 분과

[TK1-G] Reliability & Power Device

좌장: 장지원 교수(연세대학교), 김성호 교수(세종대학교)

초청발표 TK1-G-1 09:00-09:30	Study on Reliability of Automotive Semiconductor Devices and Validation Technology Trends You-Cheol Jang HL Mando
TK1-G-2 09:30-09:45	Reliability Assessment of High-voltage FinFET Technology for RF Applications Kyounghwan Oh <sup>1</sup> , Hyangwoo Kim <sup>1</sup> , Wooyeol Maeng <sup>2</sup> , Kangwook Park <sup>2</sup> , Hyung-Jin Lee <sup>2</sup> , Ju Hong Park <sup>1</sup> , and Chang-Ki Baek <sup>1</sup> <sup>1</sup> POSTECH, <sup>2</sup> Samsung Electronics Co., Ltd.
TK1-G-3 09:45-10:00	Numerical Investigation of GaN HMET Using Finite Element Method according to Process Parameters Na-Yeon Choi and Sung-Uk Zhang Digital Twin Laboratory, Dong-eui University
TK1-G-4 10:00-10:15	Simulation Study of a Full Turn-on RC-IGBT with Energy Loss Min Seok Jang <sup>1</sup> , Jee Hun Jeong <sup>1</sup> , Da Hui Yoo <sup>1</sup> , Sung Mo Koo <sup>2</sup> , and Ho Jun Lee <sup>1</sup> <sup>1</sup> Pusan National University, <sup>2</sup> TRinno Technology Co., Ltd.
TK1-G-5 10:15-10:30	Wire Bonding 두께변화와 Die-attach Void에 따른 열 저항 변화 연구 Sang Min Nam and Sung-Uk Zhang Digital Twin Laboratory, Dong-Eui University
TK1-G-6 10:30-10:45	Compact Well RC Modeling Method for P1dB and Harmonic Distortion Simulation of the Multi-stacked Transistors on RF Switch Module Nakwon Yu, Jongmin Kim, Youngchul Kim, and Hyunchul Nah DB HiTek



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Q. Metrology, Inspection, Analysis, and Yield Enhancement 분과 [TL1-Q] Metrology, Inspection, and Yield Enhancement I

좌장: 강상우 소장(한국표준과학연구원), 정용우 TL(SK 하이닉스)

초청발표 TL1-Q-1 09:00-09:30	SEM 영상을 활용한 패턴의 3차원 측정 방법 Younghoon Sohn Samsung Electronics Co., Ltd.
초청발표 TL1-Q-2 09:30-10:00	Skyrmionics Chanyong Hwang KIRSS
TL1-Q-3 10:00-10:15	Metrology/Inspection System of Extra Ultraviolet (EUV) Material and Optical Components for Ultra-fine Semiconductor Patterning Wooram Kim <sup>1</sup> , Eun Seok Choe <sup>1</sup> , Do-Yeon Hwang <sup>1</sup> , Hyo-Chang Lee <sup>1,2</sup> , Jung-Hyung Kim <sup>1</sup> , Won Chegal <sup>1</sup> , and Sang-Woo Kang <sup>1</sup> <sup>1</sup> Semiconductor Integrated Metrology Team, KRISS, <sup>2</sup> Department of Electronics and Information Engineering, Korea Aerospace University
TL1-Q-4 10:15-10:30	The Study of Optical Measurement Technologies for the Advanced Packaging of the Semiconductor Manufacturing Process Joon Ho You and Chang Soo Kim Nexensor Inc.
TL1-Q-5 10:30-10:45	Development of ARDE Technology for HARC Using IEDF based on High-resolution VSEM Etch Profile Data Jihoon Park <sup>1</sup> , Namjae Bae <sup>1</sup> , Ji-Won Kwon <sup>1</sup> , Taejun Park <sup>1</sup> , Jaemin Song <sup>2</sup> , and Gon- Ho Kim <sup>1</sup> <sup>1</sup> Seoul National University, <sup>2</sup> Samsung electronics Co., Ltd.

### 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 25일(목), 10:55-12:40 Room A(101),1층

#### B. Patterning (Lithography & Etch Technology) 분과

[TA2-B] Advanced Plasma Etching I

#### 좌장: 유신재 교수(충남대학교)

초청발표 TA2-B-1 10:55-11:30	TCAD Augmented Generative Adversarial Network for Optimizing a Chip Level Size Mask-layout Design in HARC Etching Process Hyoungcheol Kwon <sup>1</sup> , Hyunsuk Huh <sup>2</sup> , Hwiwon Seo <sup>1</sup> , Songhee Han <sup>1</sup> , Imhee Won <sup>1</sup> , Dongyean Oh <sup>1</sup> , Felipe Iza <sup>3</sup> , Seungchul Lee <sup>2</sup> , Sung Kye Park <sup>1</sup> , and Seonyong Cha <sup>4</sup> <sup>1</sup> Design Input Center, SK hynix, <sup>2</sup> Department of Mechanical Engineering, POSTECH, <sup>3</sup> The Wolfson School of Mechanical, Electrical and Manufacturing Engineering,
	Loughborough University, <sup>4</sup> R&D Devision, SK hynix
	Contact-hole Reduction Using Advanced Cyclic Etching Process in
TA2-B-2 11:30-11:45	Heptafluoropropyl Methyl Ether Plasmas 유상현 <sup>1,2</sup> , 김창구 <sup>1,2</sup> <sup>1</sup> Department of Chemical Engineering, Ajou University, <sup>2</sup> Department of Energy Systems Research, Ajou University
	Investigation of Etching Profile Transition in $SiO_2$ Etching Using Ar/CF <sub>4</sub>
TA2-B-3 11:45-12:00	Discharges 정원녕 <sup>1</sup> , 최병엽 <sup>1</sup> , 김시준 <sup>2</sup> , 이영석 <sup>2</sup> , 성인호 <sup>1</sup> , 조철희 <sup>1</sup> , 최민수 <sup>1</sup> , 설유빈 <sup>2</sup> , 이우빈 <sup>1</sup> , 서성현 <sup>1</sup> , 유신재 <sup>1,2</sup> <sup>1</sup> Department of Physics, Chungnam National University, <sup>2</sup> IQS, Chungnam National
초청발표 TA2-B-4 12:00-12:30	Plasma-Enhanced Atomic Layer Etching for Metals and Dielectric Materials Heeyeop Chae School of Chemical Engineering, Sungkyunkwan University
	Plasma Atomic Layer Etching of Titanium Nitride with Surface
TA2-B-5 12:30-12:45	Fluorination or Chlorination Heeju Ha <sup>1</sup> , Hyeongwu Lee <sup>2</sup> , Minsung Jeon <sup>3</sup> , and Heeyeop Chae <sup>1,2,3</sup> <sup>1</sup> School of Chemical Engineering, Sungkyunkwan University, <sup>2</sup> Department of Nano Science and Technology, SKKU Advanced Institute of Nanotechnology (SAINT), Sungkyunkwan University, <sup>3</sup> Department of Semiconductor Convergence Engineering, Sungkyunkwan University



2024년 1월 25일(목), 10:55-12:40 Room B(102),1층

#### H. Display and Imaging Technologies 분과

#### [TB2-H] Display and Imaging Technologies II

#### 좌장: 정예환 교수(한양대학교), 권혁인 교수(중앙대학교)

초청발표	Bio-inspired Electronic Eyes Using Flexible and Synaptic
тв2-н-1	Optoelectronics
10:55-11:25	Changsoon Choi
10.55-11.25	Center for Opto-Electronic Materials and Devices, KIST
	Effective Mg Doping in ZnO Nanoparticles via the Ultrasonic-assisted
	Synthesis for Quantum Dot Light-emitting Diodes
TB2-H-2	Hyeonseung Ban <sup>1</sup> , Yeongho Choi <sup>2,3</sup> , Hyo Geun Lee <sup>1</sup> , Woon-ho Jung <sup>2,3</sup> , Jaehoon
11:25-11:40	Lim <sup>2,3,4</sup> , and Seong-Yong Cho <sup>1</sup>
11:25-11:40	<sup>1</sup> Department of Photonics and Nanoelectronics, Hanyang University ERICA,
	<sup>2</sup> Department of Energy Science, Sungkyunkwan University, <sup>3</sup> Center for Artificial
	Atoms, Sungkyunkwan University, <sup>4</sup> SIEST, Sungkyunkwan University
	P-type Cul Stacked IGZO-TFTs with Broadband Spectrum Responsivity
TB2-H-3	Hyeon Jong Lee, Yun Sung Lee, Jong Joon Park, Gun Ho Bang, Jae Min Han, and
11:40-11:55	Sung Hun Jin
11:40-11:55	Department of Electronic Engineering, and I-Nanofab Center, Incheon National
	University
	Wavelength – Tunable Grating – Resonance InGaAs Narrowband
TB2-H-4	Photodetector with Infrared Optical PCM, Antimony Triselenide
11:55-12:10	(Sb <sub>2</sub> Se <sub>3</sub> )
11:55-12:10	Junho Jang <sup>1</sup> , II-Suk Kang <sup>2</sup> , and SangHyeon Kim <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, KAIST, <sup>2</sup> NNFC
	Analyzing the Luminance Drop and Voltage Behavior of Indium
TB2-H-5	Phosphide Quantum Dot Light-emitting Diodes
	Yeongmin Moon and Jeonghun Kwak
12:10-12:25	<sup>1</sup> Department of Electrical and Computer Engineering, Seoul National University,
	<sup>2</sup> ISRC, Seoul National University

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	ALD-Based Multinary Metal Oxide Electron Transport Layer for
	Quantum Dot Light-emitting Diodes
	Hyo Geun Lee <sup>1,2</sup> , Yong Woo Kwon <sup>2</sup> , Woon Ho Jung <sup>2</sup> , Hyeonjun Lee <sup>4</sup> , Min Seok
	Kim <sup>1</sup> , Hyun-Mi Kim <sup>5</sup> , Hyeongkeun Kim <sup>5</sup> , Hae Jin Kim <sup>6</sup> , Doh. C. Lee <sup>4</sup> , Jaehoon
TB2-H-6	Lim <sup>2,3</sup> , and Seong Yong Cho <sup>1</sup>
12:25-12:40	<sup>1</sup> Department of Photonics and Nanoelectronics, Hanyang University, <sup>2</sup> Department
	of Energy Science and Center for Artificial Atoms, Sungkyunkwan University,
	<sup>3</sup> Institute of Energy Science and Technology (SIEST), Sungkyunkwan University,
	<sup>4</sup> Department of Chemical and Biomolecular Engineering, KAIST Institute for the
	Nanocentury, KAIST, <sup>5</sup> Korea Electronics Technology Institute, <sup>6</sup> Department of
	Materials Science and Engineering, College of Engineering, Myongji University



2024년 1월 25일(목), 10:55-12:40 Room C(103),1층

#### J. Nano-Science & Technology 분과

[TC2-J] 1D/2D Optoelectronics

#### 좌장: 강기훈 교수(서울대학교), 박혜성 교수(고려대학교)

초청발표 TC2-J-1 10:55-11:25	Ultrathin Waveguides Realized with 2D Materials Myungjae Lee Seoul National University
TC2-J-2 11:25-11:40	Design and Fabrication of an In-situ Core/Shell Perovskite/MoS <sub>2</sub> Heterostructure for High-performance Photodetection Sunggyu Ryoo <sup>1</sup> , Jinwoo Sim <sup>1</sup> , Joo Sung Kim <sup>2</sup> , Juntae Jang <sup>1</sup> , Tae-woo Lee <sup>2</sup> , and Takhee Lee <sup>1</sup> <sup>1</sup> Department of Physics and Astronomy, Seoul National University, <sup>2</sup> Department of Materials Science and Engineering, Seoul National University
TC2-J-3 11:40-11:55	Electronic Trap Measurement in QD Optoelectronics Gyu Weon Hwang, Tae Hwan Park, Jun Young Jin, and Kyung Won Seo KIST
초청발표 TC2-J-4 11:55-12:25	Efficient light Manipulation Using WS <sub>2</sub> Multilayers Su-Hyun Gong Department of Physics, Korea University
TC2-J-5 12:25-12:40	An Analysis of Near-infrared Absorption in Silicon Nanowires with Wavy-sidewalls Minkeun Choi, Chang-Ki Baek, and Ju Hong Park Department of Convergence IT Engineering, POSTECH



2024년 1월 25일(목), 10:55-12:40 Room D(104),1층

P. Device for Energy (Solar Cell, Power Device, Battery, etc.) 분과 [TD2-P] 수소 생산 / 미래 에너지

좌장: 박정웅 교수(가천대학교), 유상우 교수(경기대학교)

초청발표 TD2-P-1 10:55-11:25	MOF-Based Catalysts for Efficient Electrochemical Conversion of CO <sub>2</sub> to CO Soo Young Kim Department of Materials Science and Engineering, Korea University
초청발표 TD2-P-2 11:25-11:55	Research of National Climate/Energy Policy, Strategy and R&D Planning Jeong In Lee National Climate Technology Center(NCTC), KIER
TD2-P-3 11:55-12:10	Electrochemical Nitrate Reduction to Ammonia on Facet-engineered Epitaxial Perovskite Oxide Jun Beom Hwang, Jiwoong Yang, and Sanghan Lee School of Materials Science and Engineering, GIST
TD2-P-4 12:10-12:25	Enhancing BiVO <sub>4</sub> Photoanode Performance by Insertion of an Epitaxial BiFeO <sub>3</sub> Ferroelectric Layer Yejoon Kim, Haejin Jang, and Sanghan Lee School of Materials Science and Engineering, GIST
TD2-P-5 12:25-12:40	Enhancing Zinc Cobalt Sulfide Catalysis via Heterojunction Design with Metallic Phase Molybdenum Sulfide for Water Splitting Mikiyas Mekete Meshesha <sup>1,2</sup> , Debabrata Chanda <sup>1,2</sup> , Ranjith Balu <sup>1,2</sup> , Jang Seok Gwon <sup>1,2</sup> , Shahbaz Ahmed <sup>1,2</sup> , and Bee Lyong Yang <sup>1,2</sup> <sup>1</sup> School of Advanced Materials Science and Engineering, Kumoh National Institute of Technology, <sup>2</sup> GHS Co., Ltd.

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2024년 1월 25일(목), 10:55-12:40 Room E(105),1층

E. Compound Semiconductors 분과

[TE2-E] Compound Semiconductor - High-Power Devices

좌장: 차호영 교수(홍익대학교), 문재경 교수(한국전자통신연구원)

TE2-E-1 10:55-11:10	P형 물질 (NiO <sub>x</sub> , CuO <sub>x</sub> ) 특성에 따른 α-Ga <sub>2</sub> O <sub>3</sub> PN 접합 다이오드의 항복 전 압 및 소자 특성변화 연구 Hyeon-Yeong Jeong <sup>1</sup> , Hyun-Ho Jeong <sup>1</sup> , Hyeon-Cheol Kim <sup>1</sup> , Tae Hoon Jang <sup>2</sup> , Kyu- Hwan Shim <sup>1,2</sup> , and Chel-Jong Choi <sup>1</sup> <sup>1</sup> Jeonbuk National University <sup>2</sup> R&D Division, Sigetronics, Inc.
TE2-E-2 11:10-11:25	MOCVD-grown Ga <sub>2</sub> O <sub>3</sub> -on-SiC, Ga <sub>2</sub> O <sub>3</sub> -on-Al <sub>2</sub> O <sub>3</sub> 이종 구조의 열전도도 계 측 Taeyeon Kim <sup>1</sup> , Jihyun Kim <sup>1</sup> , Jonggu Lee <sup>1</sup> , Hyeongyoon Kim <sup>2</sup> , Jihyun Park <sup>2</sup> , Daewoo Jeon <sup>2</sup> , and Jungwan Cho <sup>1</sup> <sup>1</sup> School of Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> KICET
TE2-E-3 11:25-11:40	A New Method of Forming Junction Termination Extension through Epitaxial Growth for High Voltage SiC Power Devices Sangyeob Kim, Sumin Park, Gukhwa Jeon, Jinhun Kim, Kanghee Shin, Dusan Baek, and Ogyun Seok Kumoh National Institute of Technology
TE2-E-4 11:40-11:55	Improving the Surge Characteristics of SiC MOSFETs by Using Embedded Poly-Si SBDs Gyuhyeok Kang, Yeongeun Park, Hyowon Yoon, Chaeyun Kim, Sangyeob Kim, Gukhwa Jeon, and Ogyun Seok Kumoh National Institute of Technology
TE2-E-5 11:55-12:10	Turn-on 상태의 1.2 kV SiC MOSFET 의 감마선 조사 영향 분석 김채윤 <sup>1</sup> , 윤효원 <sup>1</sup> , 박영은 <sup>1</sup> , 김상엽 <sup>1</sup> , 강규혁 <sup>1</sup> , 전국화 <sup>1</sup> , 김동석 <sup>2</sup> , 석오균 <sup>1</sup> <sup>1</sup> 금오공과대학교, <sup>2</sup> 한국원자력연구원
TE2-E-6 12:10-12:25	Crystallographic Chemical Etching Behavior of GaN Nanostructures Hyesu Ryu <sup>1</sup> , Hak-Jong Choi <sup>2</sup> , Mandar Kulkarni <sup>4</sup> , Hokyun Rho <sup>3</sup> , Ga Eun Kim <sup>1</sup> , Hyungjun Lim <sup>2</sup> , Sang Wan Ryu <sup>4</sup> , and Sang Hyun Lee <sup>1</sup> <sup>1</sup> School of Chemical Engineering, Chonnam National University, <sup>2</sup> Nano- Convergence Mechanical Systems Research Division, KIMM, <sup>3</sup> Energy Convergence Core-Facility, Chonnam National University



TE2-E-7 12:25-12:40	2kV Vertical GaN PiN Diode for High Power Device Applications Hyung-Seok Lee, Donghan Kim, Sooyoung Moon, and Sung-Bum Bae ETRI
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#### C. Material Growth & Characterization 분과

[TF2-C] Functional Oxides

#### 좌장: 유효빈 교수(서강대학교), 이재웅 교수(아주대학교)

초청발표 TF2-C-1 10:55-11:25	Functional Perovskite Oxides with Atomic Gradients Daesu Lee Department of Physics, POSTECH
TF2-C-2 11:25-11:40	Heat Management Using Mesoporous MgO for BEOL Interlayer Dielectric Anh-Duy Nguyen and Rino Choi 3D Convergence Center and Department of Materials Science and Engineering, Inha University
TF2-C-3 11:40-11:55	Fabrication of Hetero-epitaxy SrCoO <sub>2.5</sub> /SrRuO <sub>3</sub> Freestanding Thin Films for RRAM Application Eun Seok Choi and Sanghan Lee School of Materials Science and Engineering, GIST
초청발표 TF2-C-4 11:55-12:25	Surface Triggered Stabilization of Metastable Charge-ordered Phase in SrTiO <sub>3</sub> Kitae Eom Department of Electronic Engineering, Gachon University
TF2-C-5 12:25-12:40	Dielectric-constant/Capacitive Weighted Memory Materials Yoon Seok Oh <sup>1</sup> , Jun Han Lee <sup>1</sup> , Nguyen Xuan Duong <sup>2</sup> , Min-Hyoung Jung <sup>3</sup> , Hyun- Jae Lee <sup>1</sup> , Ahyoung Kim <sup>4</sup> , Youngki Yeo <sup>5</sup> , Junhyung Kim <sup>1</sup> , Gye-Hyeon Kim <sup>1</sup> , Byeong- Gwan Cho <sup>6</sup> , Jaegyu Kim <sup>5</sup> , Furqan UI Hassan Naqvi <sup>7</sup> , Jong-Seong Bae <sup>9</sup> , Jeehoon Kim <sup>10</sup> , Chang Won Ahn <sup>2</sup> , Young-Min Kim <sup>3</sup> , Tae Kwon Song <sup>11</sup> , Jae-Hyeon Ko <sup>7</sup> , Tae-Yeong Koo <sup>6</sup> , Changhee Sohn <sup>1</sup> , Kibog Park <sup>1</sup> , Chan-Ho Yang <sup>5</sup> , Sang Mo Yang <sup>4</sup> , Jun Hee Lee <sup>1</sup> , Hu Young Jeong <sup>1</sup> , and Tae Heon Kim <sup>2</sup> <sup>1</sup> UNIST, <sup>2</sup> University of Ulsan, <sup>3</sup> Sungkyunkwan University, <sup>4</sup> Sogang University, <sup>5</sup> KAIST, <sup>6</sup> Pohang Accelerator Laboratory, <sup>7</sup> Hallym University, <sup>9</sup> KBSI, <sup>10</sup> POSTECH, <sup>11</sup> Changwon National University



2024년 1월 25일(목), 10:55-12:40 Room G(201),2층

### K. Memory (Design & Process Technology) 분과 [TG2-K] RRAM and Neuromorphic Device II

#### 좌장: 최신현 교수(KAIST), 김형진 교수(인하대학교)

TG2-K-1 10:55-11:10	Selector-less V-CBRAM with High Nonlinearity and Low-power Operation via Tunnel-gap Controllable Two-Dimensional Electron Gas (2DEG) Electrode Jiho Kim, Ohhyuk Kwon, and Hyunsang Hwang POSTECH
TG2-K-2 11:10-11:25	Robust Molybdenum Disulfide Nanograined Memristors Fabricated via PECVD Process Gunhoo Woo <sup>1</sup> , Hyeong-U Kim <sup>2</sup> , Byung Chul Jang <sup>3</sup> , Jae-joon Kim <sup>4</sup> , Hocheon Yoo <sup>5</sup> , and Taesung Kim <sup>1</sup> <sup>1</sup> Sungkyunkwan University, <sup>2</sup> KIMM, <sup>3</sup> Kyungpook National University, <sup>4</sup> Seoul National University, <sup>5</sup> Gachon University
TG2-K-3 11:25-11:40	Fabrication and Resistive Switching Characterization of HfO <sub>x</sub> -Based 4- layer VRRAM for High-density Synapse Array Subaek Lee <sup>1</sup> , Sungjoon Kim <sup>2,3</sup> , Hyojin So <sup>1</sup> , Gyeongpyo Kim <sup>1</sup> , Doohyung Kim <sup>1</sup> , Minkang Kim <sup>1</sup> , Juri Kim <sup>1</sup> , Hyesung Nah <sup>1</sup> , Woo Young Choi <sup>2,3</sup> , and Sungjun Kim <sup>1</sup> <sup>1</sup> Division of Electronics and Electrical Engineering, Dongguk University, <sup>2</sup> Department of Electrical and Computer Engineering, Seoul National University, <sup>3</sup> ISRC, Seoul National University
TG2-K-4 11:40-11:55	Superior Ion Retention of Divalent Magnesium-ion Based Si/MgF <sub>2</sub> /WO <sub>x</sub> Electrochemical RAM for Neuromorphic Systems Heebum Kang, Kyumin Lee, and Hyunsang Hwang Department of Material Science and Engineering, POSTECH

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

	Implementation of Multiple-weak-filaments Type Memristor based on
	Cu:Te/ TaO <sub>x</sub> with a Te Interfacial Layer for Highly Reliable Artificial
	Synapse
	Keonhee Kim <sup>1,2,3</sup> , Jae Gwang Lim <sup>1,2,3</sup> , Sung Jae Park <sup>1,2,3</sup> , Gyutaek Oh <sup>1,4</sup> , Yeonjoo
TG2-K-5	Jeong <sup>1</sup> , Jaewook Kim <sup>1</sup> , Suyoun Lee <sup>1</sup> , Joon Young Kwak <sup>1</sup> , Jongkil Park <sup>1</sup> , Gyu Weon
11:55-12:10	Hwang <sup>1</sup> , Kyeong-Seok Lee <sup>1</sup> , Seongsik Park <sup>1</sup> , Hyun Jae Jang <sup>1</sup> , Byeong-Kwon Ju <sup>2,3</sup> ,
	Jong Keuk Park <sup>1</sup> , and Inho Kim <sup>1</sup>
	<sup>1</sup> Center for Neuromorphic Engineering, KIST, <sup>2</sup> Display and Nanosystem Laboratory,
	Korea University, <sup>3</sup> School of Electrical Engineering, Korea University, <sup>4</sup> Division of
	Electronics and Electrical Engineering, Dongguk University
	Investigating the Effect of Oxygen Vacancy Control in Sputter-
TG2-K-6	Deposited Ta <sub>2</sub> O <sub>5-x</sub> Films on Synaptic Device Properties
12:10-12:25	Chae Min Yeom <sup>1</sup> , Hyuk Min Kwon <sup>2</sup> , Hyeon Seung Lee <sup>1</sup> , and Hi Deok Lee <sup>1</sup>
	<sup>1</sup> Chungnam National University, <sup>2</sup> Semiconductor Convergence Campus of Korea
	Polytechnics College
	Artificial Neuron based on Toxic Element-free $SiO_x$ Threshold Switch
TG2-K-7	for Unconventional Oscillatory Neural Networks
12:25-12:40	Eunryeong Hong, Hyun Wook Kim, Seonuk Jeon, Nayeon Kim, and Jiyong Woo
	School of Electronic and Electrical Engineering, Kyungpook National University



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### K. Memory (Design & Process Technology) 분과 [TH2-K] DRAM

#### 좌장: 오정훈 마스터(삼성전자)

	Improvement of DRAM Cell Data Sensing Margin by Retargeting Local
초청발표 TH2-K-1 10:55-11:25	Misalignment and Process Skew Kyuseok Lee <sup>1</sup> , Jungyoung Koh <sup>1</sup> , Hyunju Sung <sup>1</sup> , Jaehyun Yu <sup>1</sup> , Hyunmi Ji <sup>1</sup> , Yeongeun Kim <sup>1</sup> , Hyewon Kim <sup>1</sup> , Jae Bum Jeon <sup>1</sup> , Jiseong Jeong <sup>1</sup> , Sunha Baek <sup>2</sup> , Ohhun Kwon <sup>2</sup> , and Jemin Park <sup>1</sup> <sup>1</sup> Semiconductor R&D Center, Samsung Electronics Co., Ltd., <sup>2</sup> Design Technology Team, Samsung Electronics Co., Ltd.
초청발표 TH2-K-2 11:25-11:55	Challenges and Issues of 2T-OC Device for DRAM Applications with Respect to Write/Read Operation and 3D Cell Architectures Dae Hwan Kang <sup>1,4</sup> , Juyoung Yun <sup>2</sup> , Suwon Seong <sup>2</sup> , Beongwoo Lee <sup>3</sup> , Junyoung Choi <sup>3</sup> , Jimin Lee <sup>3</sup> , Min-Su Cho <sup>2</sup> , Yoonyoung Chung <sup>1,2,4</sup> , Sung Woong Chung <sup>1,4</sup> , and Seyoung Kim <sup>1,3,4</sup> <sup>1</sup> Department of Semiconductor Engineering, POSTECH, <sup>2</sup> Department of Electrical Engineering, POSTECH, <sup>3</sup> Department of Materials Science and Engineering, POSTECH, <sup>4</sup> CSTC, POSTECH
ТН2-К-3 11:55-12:10	Computational Device Design of Cylindrical IGZO 2TOC DRAM Cell Sang-Mok Jeong and Sung-Min Hong School of Electrical Engineering and Computer Science, GIST
TH2-K-4 12:10-12:25	Mitigating Leakage Current Issues in 1-Row Hammer by Introducing Buried Oxide under the BCAT Structure Sang Hyun Lee, Yeon Seok Kim, Chang Young Lim, and Min-Woo Kwon Department of Electric Engineering, Gangneung-Wonju National University
TH2-K-5 12:25-12:40	A Novel 2TOC DRAM Cell Structure and Refresh Technique for Processing-in-memory Applications Seong Hwan Kong, Hui-Jae Choi, Chan-Gi Yook, and Wonbo Shim Seoul National University of Science and Technology



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#### D. Thin Film Process Technology 분과

[TI2-D] Memory Capacitors

#### 좌장: 전우진 교수(경희대학교), 이홍섭 교수(경희대학교)

	High-Performance Nanostructured Flexible Capacitor by Plasma-
초청발표	Assisted Atomic Layer Annealing at Low Temperature
TI2-D-1	Jaehyeong Lee <sup>1</sup> , Dohyun Go <sup>1</sup> , Useng Lee <sup>1</sup> , Jong. G Ok <sup>1</sup> , and Jihwan An <sup>2</sup>
10:55-11:25	<sup>1</sup> Department of Manufacturing Systems and Design Engineering, SeoulTech,
	<sup>2</sup> Department of Mechanical Engineering, POSTECH
	Low Temperature Crystallization of Atomic Layer Deposited SrTiO <sub>3</sub>
	Films with Minimal Interfacial Reactions
TI2-D-2	Hong Keun Chung <sup>1,2</sup> , Tae Joo Park <sup>2</sup> , and Seong Keun Kim <sup>1,3</sup>
11:25-11:40	<sup>1</sup> Electronic Materials Research Center, KIST, <sup>2</sup> Department of Materials Science and
	Chemical Engineering, Hanyang University, <sup>3</sup> KU-KIST Graduate School of
	Converging Science and Technology, Korea University
	Improvement of Electrical Properties of ZrO <sub>2</sub> /Al <sub>2</sub> O <sub>3</sub> Capacitors via
TI2-D-3	Interfacial Defect Control Using Ar Plasma Treatment
11:40-11:55	Hyeongjun Kim and Woongkyu Lee
11.40 11.00	Department of Green Chemistry and Materials Engineering and Department of
	Materials Science and Engineering, Soongsil University
	The Precise Control of the Interfacial Reactions in $TiO_2/RuO_2$ -
	structured Capacitors for DRAM Applications
TI2-D-4	Jihoon Jeon <sup>1,2</sup> , Taikyu Kim <sup>1</sup> , Myungsu Jang <sup>1,2</sup> , Hong Keun Chung <sup>1</sup> , and Seong
11:55-12:10	Keun Kim <sup>1,2</sup>
	<sup>1</sup> Electronic Materials Research Center, KIST, <sup>2</sup> KU-KIST Graduate School of
	Converging Science and Technology, Korea University
	Fabrication of $MoO_2$ Electrode by Thermal Atomic Layer Deposition for
TI2-D-5 12:10-12:25	High-performance TiO <sub>2</sub> -Based DRAM Capacitors
	Jae Hyeon Lee, Wangu Kang, Jeong Eun Shin, and Jeong Hwan Han
	Department of Materials Science and Engineering, Seoul National University of
	Science and Technology

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	Plasma-enhanced Atomic Layer Deposition of TiN/Mo2N Stacks for
TI2-D-6	Advanced Storage Nodes in Next-generation DRAM Capacitors
12:25-12:40	Wangu Kang, Ji Sang Ahn, Ha Young Lee, Byung Joon Choi, and Jeong Hwan Han
	Department of Materials Science and Engineering, Seoultech



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#### A. Interconnect & Package 분과

[TJ2-A] Advanced Packaging I

#### 좌장: 최광성 책임(한국전자통신연구원), 여종석 교수(연세대학교)

TJ2-A-1 10:55-11:10	A Study on the Advancement of Advanced Package Process Technology Integrating Data Analytics and Machine Learning Methods Sang Yup Lee <sup>1</sup> , Sung Hyun Yoon <sup>2</sup> , and Je Hun Youn <sup>2</sup> SK hynix
TJ2-A-2 11:10-11:25	Evaluation of Bonding Characteristics of Cu-Cu Direct Bonding through Design of Experiments (DOE) Sang Woo Park, Min Seong Jung, Yeon Ju Kim, Ji Hoon Kim, and Jong Kyung Park Department of Semiconductor Engineering, Seoul National University of Science and Technology
TJ2-A-3 11:25-11:40	The Development of Multiple Re-distribution Layer (RDL) Using FEOL Photolithography Process for the 2.xD Packaging Applications Sun Bum Kim <sup>1</sup> , Chan Seul Lee <sup>1</sup> , Gyu Lee Kim <sup>1</sup> , Sangyeun Park <sup>2</sup> , Doheon Koo <sup>2</sup> , Yeongu Choi <sup>2</sup> , Joo Young Pyun <sup>2</sup> , Chang Hoon Lee <sup>2</sup> , Hongyun So <sup>2</sup> , Kwan Kyu Park <sup>2</sup> , and Changhwan Choi <sup>1</sup> <sup>1</sup> Division of Materials Science and Engineering, Hanyang University, <sup>2</sup> Department of Mechanical Engineering, Hanyang University
초청발표 TJ2-A-4 11:40-12:10	Low Temperature Cu-Cu Direct Bonding: A Key Technology in Advanced Semiconductor Packaging Technology Ju-Young Kim, Ji-Youn Kwak, and Youngju Sim UNIST
초청발표 TJ2-A-5 12:10-12:40	Global No.1 HBM2E, HBM3의 품질/수율 경쟁력 동시 확보 Look Back 및 차세대 제품에서의 도전 과제 Sung Woo Ma, Jin Hee Lee, and Woong-sun Lee WLP Technology Group, SK hynix

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G. Device & Process Modeling, Simulation and Reliability 분과

[TK2-G] Carrier Transport & Ab-initio Simulation

#### 좌장: 정창욱 교수(울산과학기술원), 장지원 교수(연세대학교)

TK2-G-1 10:55-11:10	Neural Network-Assisted Acceleration of Full-Band Semi-Classical
	Monte Carlo Carrier Transport Simulation Dong Hyeok Lee <sup>1</sup> and Jiwon Chang <sup>1,2</sup>
	<sup>1</sup> Department of Materials Science and Engineering, Yonsei Universit, <sup>2</sup> Department of System Semiconductor Engineering, Yonsei University
TK2-G-2 11:10-11:25	Cation Disorder Limited IGZO Mobility Calculation based on Density Functional Theory Seung Hyo Han, Deokhwa Seo, and Mincheol Shin School of Electrical Engineering, KAIST
TK2-G-3 11:25-11:40	Effects of the Gate Offset on Gate-all-around Negative Capacitance Field Effect Transistors with Self-heating Effect Yangjin Jung, Hyeongu Lee, and Mincheol Shin Department of Electrical Engineering, KAIST
	Semi-Classical Monte Carlo Simulation of Electron/Hole Mobility in
TK2-G-4 11:40-11:55	Monolayer MX <sub>2</sub> (M=Mo, W; X=S, Se) Sukhyeong Youn <sup>1,2</sup> , Donghyeok Lee <sup>1,2</sup> , and Jiwon Chang <sup>1,2</sup> <sup>1</sup> Department of System Semiconductor Engineering, Yonsei University, <sup>2</sup> Department of Materials Science & Engineering, Yonsei University
	Study of Non-equilibrium Energetics in Van der Waals Ferroelectric
TK2-G-5 11:55-12:10	Tunnel Junctions Using Multi-space Density Functional Theory Kaptan Rajput, Ryong Gyu Lee, Tae Hyung Kim, and Yong-Hoon Kim School of Electrical Engineering, KAIST
TK2-G-6 12:10-12:25	Strain-Tuned Ferroelectric Transitions in HfO2: A New Pathway to
	Ferroelectric Devices II Young Lee <sup>1,2</sup> and Jae Jun Yu <sup>1,2</sup> <sup>1</sup> Center for Theoretical Physics, Seoul National University, <sup>2</sup> Department of Physics
	and Astronomy, Seoul National University

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	Transport Simulation for Nanosheet FET with Extended Source and
TK2-G-7	Drain Regions
12:25-12:40	Phil-Hun Ahn and Sung-Min Hong
	School of Electrical Engineering and Computer Science, GIST



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#### V. Quantum Technology 분과

#### [TL2-V] AMO-based Quantum Technology

좌장: 이문주 교수(POSTECH)

초청발표 TL2-V-1 10:55-11:25	A Chip-scale Rb Two-photon Optical Clock Hyun-Gue Hong Time and Frequency Group, KRISS Dark Resonances and Temperature Estimation of a Trapped-ion Qubit
TL2-V-2 11:25-11:40	Hyegoo Lee, Keumhyun Kim, Noa Jeong, Yongha Shin, Myunghun Kim, Junhee Cho, and Moonjoo Lee Electrical Engineering, POSTECH
TL2-V-3 11:40-11:55	Coherent Control of an Optical Trapped-ion Qubit Keumhyun Kim, Hyegoo Lee, Yongha Shin, Noa Jeong, Myunghun Kim, Junhee Cho, and Moonjoo Lee Department of Electrical Engineering, POSTECH
TL2-V-4 11:55-12:10	Exploring Third-order Exceptional Point in An Ion-Cavity System Jinuk Kim <sup>2</sup> , Taegyu Ha <sup>1</sup> , Donggeon Kim <sup>1</sup> , Dowon Lee <sup>1</sup> , Ki-Se Lee <sup>1</sup> , Jongcheol Won <sup>1</sup> , Yougil Moon <sup>1</sup> , and Moonjoo Lee <sup>1</sup> <sup>1</sup> Department of Electrical Enginnering, POSTECH, <sup>2</sup> Department of Physics, Yale University
TL2-V-5 12:10-12:25	Chaotic Motion of a Trapped-Ion Nonlinear Mechanical Oscillator Myunghun Kim, Junhee Cho, Sehyeon Gwon, Keumhyun Kim, Hyegoo Lee, and Moonjoo Lee Department of Electrical Engineering, POSTECH
TL2-V-6 12:25-12:40	Microfabrication of an Ion Trap Chip with Prevention of Direct Silicon Exposure of Sidewalls to Alleviate Laser-induced Charging SeungWoo Yoo <sup>1,2,3</sup> , KwangYeul Choi <sup>1,2,3</sup> , Suhan Kim <sup>1,2,3</sup> , Chiyoon Kim <sup>1,2,3</sup> , Changhyun Jung <sup>1,2,3</sup> , Roberts Berkis <sup>4</sup> , Tracy E. Northup <sup>4</sup> , and Taehyun Kim <sup>1,2,3</sup> <sup>1</sup> Department of Computer Science and Engineering, Seoul National University, <sup>2</sup> Automation and System Research Institute, Seoul National University, <sup>3</sup> ISRC, Inter-university Semiconductor Research Center, Seoul National University, <sup>4</sup> Alnstitut für Experimentalphysik, Universität Innsbruck



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#### B. Patterning (Lithography & Etch Technology) 분과

[TA3-B] Advanced Plasma Etching II

좌장: 채희엽 교수(성균관대학교)

초청발표 TA3-B-1 15:30-16:00	<b>나노식각 공정진단·제어기술 Real-Time PI-VM 소개</b> 김곤호 <sup>1,2</sup> <sup>1</sup> 서울대학교 원자핵공학과, <sup>2</sup> 서울대학교 플라즈마 응용연구실
TA3-B-2 16:00-16:15	OLED 디스플레이 제조를 위한 다중 금속막 식각 공정의 PI-VM 기반 패턴 제어 박윤아 <sup>1</sup> , 노연길 <sup>1</sup> , 서라벌 <sup>1</sup> , 송봉섭 <sup>1</sup> , 김곤호 <sup>2</sup> , 박설혜 <sup>1</sup> <sup>1</sup> 삼성디스플레이, <sup>2</sup> 서울대학교
TA3-B-3 16:15-16:30	Enhancement of Plasma Uniformity in Adaptive Dry Etcher with Convex-Shaped Electrodes Sanghyun Kang <sup>1</sup> , Seokchan Yoon <sup>2</sup> , Jaehyuk Lim <sup>1</sup> , and Changhwan Shin <sup>2</sup> <sup>1</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University, <sup>2</sup> School of Electrical Engineering, Korea University
TA3-B-4 16:30-16:45	Observation of the Floating Sheath Distribution Adjacent to a DC- biased Metal Substrate NamJae Bae <sup>1</sup> , Nam-Kyun Kim <sup>2</sup> , Haneul Lee <sup>1</sup> , Yunchang Jang <sup>2</sup> , Seolhye Park <sup>3</sup> , and Gon-Ho Kim <sup>1</sup> <sup>1</sup> Seoul University, <sup>2</sup> Samsung Electronics Co., Ltd., <sup>3</sup> Samsung Display Co., Ltd.
TA3-B-5 16:45-17:00	Nickel-silicide Alloy as an Alternative to Noble Metal Catalyst for Metal-assisted Chemical Etching of Si Haekyun Bong, Kyunghwan Kim, Sunhae Choi, and Jungwoo Oh School of Integrated Technology, Yonsei University
TA3-B-6 17:00-17:15	Correlation with the Microstructure and Synergistic Physiochemical Etching Resistance of Nanocomposites under CF <sub>4</sub> /Ar/O <sub>2</sub> Plasma Conditions in Plasma Etching Chambe Ho Jin Ma <sup>1</sup> , Mi-Ju Kim <sup>1</sup> , Ha-Neul Kim <sup>1</sup> , Jae-Woong Ko <sup>1</sup> , Jae-Wook Lee <sup>1</sup> , Hyo-Chang Lee <sup>2</sup> , and Young-Jo Park <sup>1</sup> <sup>1</sup> KIMS, <sup>2</sup> Korea Aerospace University

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#### H. Display and Imaging Technologies 분과

#### [TB3-H] Display and Imaging Technologies III

#### 좌장: 하만륜 상무(DB하이텍), 이재규 마스터(삼성전자)

TB3-H-1 15:30-15:45	Monolithic Integration of a-IGZO TFT and p-i-n a-Si:H Photodiode for
	Ultra Flexible and Semi-Transparent Image Sensors
	Donghyeong Choi <sup>1,2</sup> , Jong-Won Yoon <sup>1</sup> , and Yonghun Kim <sup>1</sup>
13.30 13.43	<sup>1</sup> Department of Energy & Electronic Materials, Surface & Nano Materials Division,
	KIMS, <sup>2</sup> School of Materials Science and Engineering, Pusan National University
	Noise Suppression Techniques for Low-Noise CMOS Image Sensors
TB3-H-2	Gihwan Cho, Min-Woong Seo, Masamichi Ito, Sung-Jae Byun, Hyukbin Kwon,
15:45-16:00	Sanggwon Lee, Daehee Bae, Heesung Shim, Jae-Kyu Lee, and Chang-Rok Moon
	Semiconductor R&D Center, Samsung Electronics Co., Ltd.
TB3-H-3	Partitioned CMS 기법을 이용한 저잡음 이미지 센서 윤수연, 김수연
16:00-16:15	프루고, 펌루고   동국대학교 반도체과학과
	Improvement of Dark Current Caused by Thermionic Emission in
TB3-H-4	Voltage-Domain Global Shutter CMOS Image Sensor
16:15-16:30	Jae-Hoon Jeon, Je-Yeoun Jung, Sangyoon Kim, Seung-Sik Kim, Jae-Kyu Lee, and
	Chang-Rok Moon
	Semiconductor R&D Center, Samsung Electronics Co., Ltd.
	Guard-ring Additional Implantation Technique for Reducing Dark Count
TB3-H-5	Rate of Single-photon Avalanche Diode
16:30-16:45	Sang-Hwan Kim, Juhwan Jung, Hangyu Lee, Dongil Kim, Changhun Han, Taewook
	Kang, Chulwoo Hwang, Harin Kang, Dongha Lee, Manlyun Ha and Yongchan Kim
	Technology Development Team 4, DB Hitek
TB3-H-6 16:45-17:00	640 x 480 In-direct Time-of-Flight Sensor 개발을 위한 5.0um Pixel 설
	Л
	Jaehyung Jang , Hoon-moo Choi , Jongchae Kim , Kyungsu Byun , Kyundo Kim ,
	Minseok Shin , Hoon-sang Oh , and Chang-rock Song
	CIS Development, SK hynix Inc.

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TB3-H-7 17:00-17:15	A Backside-Illumination Technique to Enhance Near-Infrared Photon
	Detection Probability of Single-Photon Avalanche Diode
	Sang-Hwan Kim, Juhwan Jung, Hangyu Lee, Dongil Kim, Changhun Han, Chulwoo
	Hwang, Harin Kang, Dongha Lee, and Manlyun Ha
	Technology Development Team 4, DB Hitek



2024년 1월 25일(목), 15:30-17:15 Room C(103),1층

#### M. RF and Wireless Design 분과

[TC3-M] RF and Wireless Design

#### 좌장: 권구덕 교수(강원대학교), 한정환 교수(충남대학교)

TC3-M-1 15:30-15:45	N-path Filter-Based Wideband CMOS Low-Noise Amplifier Juhui Jeong, Yujung Kim, Junhyeop Kim, and Junghwan Han Department of Radio and Information Communications Engineering, Chungnam National University
초청발표	Analog Circuits in Samsung S.LSI
TC3-M-2	Seunghyun Oh
15:45-16:15	Samsung Electronics Co., Ltd.
초청발표	0.15um GaN HEMT 소자 및 MMIC PDK 개발
TC3-M-3	강동민
16:15-16:45	한국전자통신연구원 RF/전력부품연구실
초청발표 TC3-M-4 16:45-17:15	Introduction to High Performance LO Design Techniques in Modern Wireless Communication Systems Shinwoong Kim Handong Global University



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F. Silicon and Group-IV Devices and Integration Technology 분과 [TD3-F] Advanced Device Technology

좌장: 김경록 교수(울산과학기술원), 이용규 마스터(삼성전자)

초청발표	Analog Neuron Devices for Hardware-Based Spiking Neural Networks
TD3-F-1	Sung Yun Woo
15:30-16:00	School of Electronic and Electrical Engineering, Kyungpook National University
초청발표	Design and Fabrication of CMOS Compatible Dual Gate Synapse Array
TD3-F-2	Myung-Hyun Ba
16:00-16:30	Gangneung-Wonju National University
초청발표	Ferroic Field Effect Transistor for Low-Power Logic Technology
TD3-F-3	Sihyun Kim
16:30-17:00	Department of Electronic Engineering, Sogang University
TD3-F-4	* 특허청 특별발표
17:00-17:15	최첨단 초미세 반도체 소자 집적 기술 특허 동향 및 국가별 출원 집중도 분석 결과



2024년 1월 25일(목), 15:30-17:15 Room E(105),1층

N. VLSI CAD 분과 [TE3-N] AI to VLSI CAD

좌장: 송대건 교수(경북대학교)

초청발표 TE3-N-1 15:30-16:00	Ternary VLSI Design: A Circuits and Systems Perspective Sunmean Kim School of Electronic and Electrical Engineering, Kyungpook National University
TE3-N-2 16:00-16:15	Artificial Schematic Creator with Generative Model Yewon Hwang, Jakang Lee, and Seokhyeong Kang POSTECH
TE3-N-3 16:15-16:30	Design-technology Co-optimization for Standard Cell Pin Length Modulation Junghyun Yoon and Heechun Park Kookmin University
TE3-N-4 16:30-16:45	Impact Analysis of Coupling Effect Induced by Through-silicon Via for Static Timing Analysis in 3D IC Euntaek Oh, Mujun Choi, and Juho Kim Sogang University
TE3-N-5 16:45-17:00	Pin Accessibility Aware Routability Prediction Using Graph Neural Network Jiyun Park, Jongho Yoon, and Seokhyeong Kang POSTECH
TE3-N-6 17:00-17:15	Unsupervised Learning-Based Legalization with Graph Neural Network Dho Ui Lim and Heechun Park Kookmin University



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I. MEMS & Sensor Systems 분과

[TF3-I] Recent Advances in MEMS

좌장: 강주훈 교수(성균관대학교)

초청발표 TF3-I-1 15:30-16:00	Evaporative Cooling-Based, Power-efficient Thermal Systems for Skin-interfaced Bioelectronic Devices Minsu Park Dankook University
초청발표 TF3-I-2 16:00-16:30	실시간 다중 감지 가능한 3차원 통합형 생체모사 전자 피부 시스템 이보연 KIMM
TF3-I-3 16:30-16:45	Design of Wireless Flexible Smart Gloves for Controlling Virtual and Augmented Reality Lurong Yang and Jeonghyun Kim Department of Electronic Convergence Engineering, Kwangwoon University
TF3-I-4 16:45-17:00	Sweat Permeable and Wearable Electronic Skins with All-inorganic Opto-devices for Long-term Photoplethysmogram Signal Monitoring Jeong Hyeon Kim <sup>1,2</sup> and Han Eol Lee <sup>1,2</sup> <sup>1</sup> Division of Advanced Materials Engineering, Jeonbuk National University, <sup>2</sup> Department of JBNU-KIST Industry-Academia Convergence Research, Jeonbuk National University
TF3-I-5 17:00-17:15	Use of Composite Materials in Flexible Sensors Wooseok Kim and Sang Min Won Sungkyunkwan University

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 25일(목), 15:30-17:15 Room G(201),2층

## K. Memory (Design & Process Technology) 분과 [TG3-K] RRAM and Neuromorphic Device III

#### 좌장: 김성준 교수(동국대학교), 권민우 교수(강릉원주대학교)

TG3-K-1 15:30-15:45	Optimized Chalcogenide Medium for Inherently Activated Resistive Switching Device Jin Joo Ryu <sup>1,2</sup> , Taeyong Eom <sup>1</sup> , Hyunchul Sohn <sup>2</sup> , and Gun Hwan Kim <sup>2,3</sup> <sup>1</sup> Thin Film Materials Research Center, KRICT, <sup>2</sup> Department of Materials Science and Engineering, Yonsei University, <sup>3</sup> Department of System Semiconductor Engineering, Yonsei University			
TG3-K-2 15:45-16:00	Pseudo Synaptic Sampling: Energy-Efficient Algorithm for Spiking Hyunwoo Kim, Suyeon Jang, Uicheol Shin, and Sangbum Kim Department of Material Science and Engineering, Seoul National University			
TG3-K-3 16:00-16:15	Design and Hardware Implementation of Memristive Based Neural Networks for Efficient Neuromorphic Computing Jae Gwang Lim <sup>1,2</sup> , Keonhee Kim <sup>1,2</sup> , Sung Jae Park <sup>1,2</sup> , Gyutaek Oh <sup>1</sup> , Yeonjoo Jeong <sup>1</sup> , Jaewook Kim <sup>1</sup> , Su youn Lee <sup>1</sup> , Joon Young Kwak <sup>1</sup> , Jongkil Park <sup>1</sup> , Gyu Weon Hwang <sup>1</sup> , Kyeong-Seok Lee <sup>1</sup> , Seongsik Park <sup>1</sup> , Hyun Jae Jang <sup>1</sup> , Byeong-Kwon Ju <sup>2</sup> , Jong Keuk Park <sup>1</sup> , and Inho Kim <sup>1</sup> <sup>1</sup> Center for Neuromorphic Engineering, KIST, <sup>2</sup> Display and Nanosystem Laboratory, School of Electrical Engineering, Korea University			
TG3-K-4 16:15-16:30	Implementing a Scalable Neural Network at the Device Level Using a 3D Vertical Structure for PIM Seojin Cho, Hyejin Kim, Minsu Kang, Sooho Kim, Sion Kim, Yuna Kim, and Daeseok Lee Department of Electronic Materials Engineering, Kwangwoon University			
TG3-K-5 16:30-16:45	Unipolar and Bipolar 1S1M-Based MC-Dropconnect Hardware Implementation Do Hoon Kim, Woon Hyung Cheong, Hanchan Song, Jae Bum Jeon, and Kyung Min Kim KAIST			

	Effect of the $SiO_2$ Film Formation Process on the Recognition Rate in
ТG3-К-6 16:45-17:00	$\label{eq:pd/IGZO/SiO_2/p^+-Si} \mbox{ Memristors for Artificial Neural Network}$
	Application
	Dong Hyeop Shin, Seung Joo Myoung, Changwook Kim, Jong-Ho Bae, Sung-Jin
	Choi, Dong Myong Kim, and Dae Hwan Kim
	School of Electrical Engineering, Kookmin University
	Sound Localization Using Brain-inspired Memristive Delay System for
TG3-K-7	Active Speaker Detection
17:00-17:15	Hanchan Song, Mingu Lee, Woojoon Park, Gwangmin Kim, and Kyung Min Kim
	Department of Materials Science and Engineering, KAIST



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### S. Chip Design Contest 분과

[TH3-S] Chip Design Contest

#### 좌장: 조건희 교수(경북대학교), 장영찬 교수(금오공과대학교)

TH3-S-1 15:30-15:45	Design of Single-ended PAM-3 Transmitter with Crosstalk Cancellation Scheme for Memory Interface Dongwoo Kang and Kwanseo Park Yonsei University
TH3-S-2 15:45-16:00	Design Points of Period-modulation Capacitance-to-digital Converter for Continuous Glucose Monitoring System Donghyun Youn and Minkyu Je School of Electrical Engineering, KAIST
TH3-S-3 16:00-16:15	A Four-phase Time-Based Switched-Capacitor LDO With 13-ns Settling Time at 0.5-V Input for Energy-efficient Computing in SoC Applications Hyunjin Kim, Taehyeong Park, and Chulwoo Kim Department of Semiconductor System Engineering, Korea University
TH3-S-4 16:15-16:30	Hardware Implementation of a CNN-based Accurate and Efficient 3D Hand Pose Estimator Yongsoo Kim <sup>1</sup> , Wencan Chen <sup>2</sup> , Jaehyeon So <sup>3</sup> , Siyeon Kim <sup>3</sup> , Chanwook Hwang <sup>3</sup> , Jong Hwan Ko <sup>3</sup> , and Jaehyuk Choi <sup>3</sup> <sup>1</sup> Department of Semiconductor and Display Engineering, Sungkyunkwan University, <sup>2</sup> Department of Artificial Intelligence, Sungkyunkwan University, <sup>3</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University



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## D. Thin Film Process Technology 분과

### [TI3-D] Ferroelectrics

#### 좌장: 최병준 교수(서울과학기술대학교), 김건환 교수(연세대학교)

TI3-D-1 15:30-15:45	Mitigation of Field-driven Dynamic Phase Evolution in Ferroelectric Hf <sub>0.5</sub> Zr <sub>0.5</sub> O <sub>2</sub> Films by Adopting Oxygen-supplying Electrode Younghwan Lee <sup>1</sup> , Se Hyun Kim <sup>2</sup> , Hyun Woo Jeong <sup>2</sup> , Geun Hyeong Park <sup>2</sup> , Jaewook Lee <sup>2</sup> , Young Yong Kim <sup>3</sup> , and Min Hyuk Park <sup>1,2</sup>
	<sup>1</sup> Research Institute of Advanced Materials, Seoul National University, <sup>2</sup> Department of Materials Science and Engineering, Seoul National University, <sup>3</sup> Beamline Division, Pohang Accelerator Laboratory
	Interface Engineering for Enhancement of Ferroelectricity in Sub-5 nm
TI3-D-2	Ultrathin Hf <sub>0.5</sub> Zr <sub>0.5</sub> O <sub>2</sub> Films
15:45-16:00	Se Hyun Kim <sup>1</sup> , Younghwan Lee <sup>2</sup> , Dong Hyun Lee <sup>1</sup> , and Min Hyuk Park <sup>1,2</sup>
	<sup>1</sup> Department of Mcrystaterials Science and Engineering, Seoul National University, <sup>2</sup> Research Institute of Advanced Materials, Seoul National University
	Synergistic Impact of $AI_2O_3$ Capping Layer and Deposition
	Temperature for Enhancing the Ferroelectricity of Undoped HfO <sub>2</sub> Thin
TI3-D-3	Films
16:00-16:15	Sang Han Ko and Sung Min Yoon Department of Advanced Materials Engineering for Information and Electronics,
	Kyung Hee University
	CF₄ Plasma Passivation on Laminated-ALD HZO MFIS-FeFET
TI3-D-4	Kyungsoo Park <sup>1</sup> , Chulwon Chung <sup>2</sup> , Boncheol Ku <sup>1</sup> , Seung Hyeon Yun <sup>1</sup> , Junhyeok Park <sup>1</sup> , Yu Jeong Choi <sup>1</sup> , and Changhwan Choi <sup>1</sup>
16:15-16:30	<sup>1</sup> Division of Materials Science and Engineering, Hanyang University, <sup>2</sup> Deparment of
	Energy Engineering, Hanyang University
	Development of Lab-Scale Pulsed Laser Annealing (PLA) System for
TI3-D-5	$Hf_xZr_{1-x}O_2$ Thin Film Crystallization
16:30-16:45	Hyeonsik Kim <sup>1,2</sup> , Hyojin Yang <sup>2</sup> , Sejun Park <sup>2</sup> , Jong-Ho Bae <sup>2</sup> , and Inhee Cho <sup>1</sup>
	<sup>1</sup> Korea-Russia Innovation Center, KITECH, <sup>2</sup> School of Electrical Engineering, Kookmin University

TI3-D-6	Ferroelectricity of Hf <sub>0.5</sub> Zr <sub>0.5</sub> O <sub>2</sub> Thin Film Induced at 350 °C by Thermally
	Accelerated Nucleation during Atomic Layer Deposition Jaewook Lee <sup>1,2</sup> , Se Hyun Kim <sup>1,2</sup> , Younghwan Lee <sup>3</sup> , Sang-Youn Park <sup>4</sup> , and Min
16:45-17:00	Hyuk Park <sup>1,2,3</sup> <sup>1</sup> Department of Materials Science and Engineering, Seoul National Universit <sup>2</sup> Inter-University Semiconductor Research Center, Seoul National Universit <sup>3</sup> Research Institute of Advanced Materials College of Engineering, Seoul Nation University, <sup>4</sup> Pohang Accelerator Laboratory, POSTECH
	The Impact of CF4 Plasma Treatment on the Performance of
TI3-D-7	HfO <sub>2</sub> /IGZO Thin film Transistors (TFTs)
17:00-17:15	Gyu Lee Kim, Sun bum Kim, Chan seul Lee, and Changhwan Choi
	Division of Materials Science and Engineering, Hanyang University



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## A. Interconnect & Package 분과

[TJ3-A] Hybrid Bodning Technology

#### 좌장: 이태익 선임(한국생산기술연구원), 이은호 교수(성균관대학교)

TJ3-A-1 15:30-15:45	Novel Method of Direct Cu Bonding Using Chemical Reducing Agents Jeehoo Na <sup>1,2</sup> , Eunhye Lee <sup>1</sup> , So Jeong Lee <sup>1</sup> , Dongwoo Lee <sup>2</sup> , and Tae-Ik Lee <sup>1</sup> <sup>1</sup> Micro-Joining Center, Joining R&D Group, KITECH, <sup>2</sup> Applied Mechanics and Materials Design Lab, School of Mechanical Engineering, Sungkyunkwan University			
TJ3-A-2 15:45-16:00	Study on Employment of Au Film for Cu-Cu Low Temperature Bonding Ha-Hyung Pin <sup>1</sup> , Hyun-Dong Lee <sup>1</sup> , Hoon Choi <sup>1</sup> , Ju-Hyeon Kim <sup>3</sup> , and Hoo-Jeong Lee <sup>1,2,3</sup> <sup>1</sup> Department of Smart Fab. Technology, Sungkyunkwan University, <sup>2</sup> Department of Advanced Materials Science & Engineering, Sungkyunkwan University, <sup>3</sup> Department of Semiconductor Convergence Engineering, Sungkyunkwan University			
TJ3-A-3 16:00-16:15	하이브리드 본딩 기술 적용을 위한 저온 Cu-Cu 및 SiO <sub>2</sub> -SiO <sub>2</sub> 접합부의 정 량적 계면접착에너지 평가 및 분석 권용범 <sup>1,2</sup> , 김가희 <sup>1,2</sup> , 김사라은경 <sup>3</sup> , 박영배 <sup>1,2</sup> <sup>1</sup> 안동대학교 신소재공학부, <sup>2</sup> 안동대학교 청정에너지소재기술연구센터, <sup>3</sup> 서울과학기술대학교 지능형반도체공학과			
TJ3-A-4 16:15-16:30	구리/폴리머 하이브리드 본딩을 위한 화학적기계연마 기술 강석경 <sup>1</sup> , 박주성 <sup>2</sup> , 전찬수 <sup>2</sup> , 김경민 <sup>2</sup> , 김산하 <sup>1</sup> <sup>1</sup> Department of Mechanical Engineering, KAIST, <sup>2</sup> Department of Material Science and Engineering, KAIST			
TJ3-A-5 16:30-16:45	A Parametric Approach on HBM Hybrid Bonding Process Jae-Uk Lee <sup>1</sup> , Sung-Hyun Oh <sup>1</sup> , Sarah-Eunkyung Kim <sup>2</sup> , Hoo-Jeong Lee <sup>1</sup> , and Eun-Ho Lee <sup>1</sup> <sup>1</sup> Sungkyunkwan University, <sup>2</sup> Seoul National University of Science of Technology			
TJ3-A-6 16:45-17:00	Effect of Cu Pad Density on Cu/SiCN Hybrid Bonding: A Finite Element Analysis Study So-Yeon Park <sup>1</sup> , Hyunji Yoon <sup>1</sup> , Cha-Hee Kim <sup>1</sup> , Sarah Eunkyung Kim <sup>2</sup> , and Won-Jun Lee <sup>1</sup> <sup>1</sup> Department of Nanotechnology and Advanced Materials Engineering, Sejong University, <sup>2</sup> Department of Semiconductor Engineering, Seoul National University of Science and Technology			

TJ3-A-7 17:00-17:45	Enhancing S	i-b	ridge Performa	ance: A Stud	ly on Signal	Integrity and
	Structural Op	otin	nization			
	Ji Hoon Kang a	nd	Kee-Won Kwon			
17.00-17.43	Department o	of	Semiconductor	Convergence	Engineering,	Sungkyunkwan
	University					

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 25일(목), 15:30-17:15 Room K(205),2층

G. Device & Process Modeling, Simulation and Reliability 분과 [TK3-G] TCAD & Multiphysics Simulation

#### 좌장: 이재우 교수(고려대학교), 김현우 교수(건국대학교)

TK3-G-1 15:30-15:45	The Quantum Mechanical Effect of Amorphous InGaZnO Transistors
	Compared with Silicon-on Insulator Transistors
	Ho Jung Lee, Donguk Kim, Changwook Kim, Dong Myong Kim, Sung-Jin Choi,
	Jong-Ho Bae, and Dae Hwan Kim
	School of Electrical Engineering, Kookmin University
	Investigating Radioactive Ions Effect in The Complementary FET
TK3-G-2	based on The Structure
15:45-16:00	Jonghwa Jeong and Hyunwoo Kim
	Department of Electrical and Electronics Engineering, Konkuk University
	Mitigation of Single Event Upset Effects in 3 nm Technology Node
TK3-G-3	Gate-All-Around Nanosheet FET 6T SRAM cell
16:00-16:15	Minji Bang, Jonghyeon Ha, Minki Suh, Dabok Lee, Minsang Ryu, and Jungsik Kim
	Department of Electrical Engineering, Gyeongsang National University
	A Novel CT-DRAM with High Speed and High Retention at Low Power
TK3-G-4	to Replace DRAM
16:15-16:30	Dabok Lee, Jonghyeon Ha, Minki Suh, Minji Bang, Minsang Ryu, and Jungsik Kim
	Department of Electrical Engineering, Gyeongsang National University
	Investigation of Filamentary Resistive Switching Using Finite Element
TK3-G-5	Method with Phase-field and Multiphysics Simulation
16:30-16:45	Dongmyung Jung and Yongwoo Kwon
	Department of Materials Science and Engineering, Hongik university
	Computational Investigation on Quantum Information Processing
TK3-G-6	Using Triple Quantum Dot Structures
16:45-17:00	Ji-Hoon Kang and Hoon Ryu
	KISTI
	Multiphysics Modeling of Thermal Disturbance in Three-Dimensional
TK3-G-7	Stackable Phase-Change Memory
17:00-17:15	Yechan Kim <sup>1</sup> , Namwook Hur <sup>2</sup> , Joonki Suh <sup>2</sup> , and Yongwoo Kwon <sup>1</sup>
	<sup>1</sup> Hongik University, <sup>2</sup> Ulsan National Institute of Science and Technology



2024년 1월 25일(목), 15:30-17:15 Room L(206),2층

### V. Quantum Technology 분과

[TL3-V] Solid State Quantum Technology

좌장: 이동헌 교수(고려대학교), 차진웅 선임연구원(표준과학연구원)

초청발표 TL3-V-1 15:30-16:00	Cryo-CMOS Controller for Superconducting Quantum Processor Jae-Yoon Sim POSTECH
초청발표 TL3-V-2 16:00-16:30	Fast Calibration and Error Mitigation Applied to Spin Qubits in Silicon Dohun Kim <sup>1,2</sup> <sup>1</sup> Department of Physics and Astronomy, Seoul National University, <sup>2</sup> Institute of Applied Physics, Seoul National University
TL3-V-3 16:30-16:45	Implementation of Zero-noise Extrapolation in <sup>28</sup> Si/SiGe Spin Qubits Jaewon Jung <sup>1</sup> , Hanseo Sohn <sup>1</sup> , Jaemin Park <sup>1</sup> , Hyeongyu Jang <sup>1</sup> , Lucas E. A. Stehouwer <sup>2</sup> , Davide Degli Esposti <sup>2</sup> , Giordano Scappucci <sup>2</sup> , and Dohun Kim <sup>1</sup> <sup>1</sup> Department of Physics and Astronomy, Seoul National University, <sup>2</sup> QuTech and Kavli Institute of Nanoscience, Delft University of Technology
TL3-V-4 16:45-17:00	Closed-loop Feedback and Sensor Dot Decoupling Technique for Suppressing Charge Noise in <sup>28</sup> Si/SiGe Spin Qubit Hyeongyu Jang <sup>1</sup> , Jaemin Park <sup>1</sup> , Hanseo Sohn <sup>1</sup> , Lucas E. A. Stehouwer <sup>2</sup> , Davide Degli Esposti <sup>2</sup> , Giordano Scappucci <sup>2</sup> , and Dohun Kim <sup>1</sup> <sup>1</sup> Department of Physics and Astronomy, Seoul National University, <sup>2</sup> QuTech and Kavli Institute of Nanoscience, Delft University of Technology
TL3-V-5 17:00-17:15	A Multi-physics Analysis to Calculate Energy Dissipation in Superconducting Qubit Systems with Continuum Mechanics Sung-Hyun Oh <sup>1</sup> , Kyoung-Won Kim <sup>3</sup> , and Eun-Ho Lee <sup>1,2</sup> <sup>1</sup> Department of Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> Department of Smart Fab. Technology, Sungkyunkwan University, <sup>3</sup> Keysight Technologies Korea Ltd.



2024년 1월 26일(금), 09:00-10:45 Room A(101),1층

## B. Patterning (Lithography & Etch Technology) 분과

[FA1-B] Lithography and photoresist I

좌장: 성명모 교수(한양대학교), 이진균 교수(인하대학교)

초청발표 FA1-B-1 09:00-09:30	Spin on Hardmask(SOC)의 소재 개발 동향 및 특성 Jin Gon Kim SKMP	
FA1-B-2 09:30-09:45	Advanced Exposure Technology in ArF Immersion Photolithography Jungchul Song <sup>1,2</sup> , Gyu-Won Han <sup>1</sup> , Jeonghwan Kim <sup>3</sup> , and Ga-Won Lee <sup>2</sup> <sup>1</sup> NNFC, <sup>2</sup> Division of Electronics Engineering, Chungnam National University, <sup>3</sup> SK Materials Performance	
FA1-B-3 09:45-10:00	Multi Patterning Technique for Small Pitch of Logic Interconnection Chanhoo Park, Minkwon Choi, Hyejun Jin, Jeong Hoon Ahn, and Jong-Ho Lee Foundry Business, Samsung Electronics Co., Ltd.	
초청발표 FA1-B-4 10:00-10:30	At Wavelength EUV Metrology and Inspection Technologies Sangsul Lee <sup>1</sup> , <sup>2</sup> , Jiho Kim <sup>1</sup> , and Geonhwa Kim <sup>1</sup> <sup>1</sup> Pohang Accelerator Laboratory, POSTECH, <sup>2</sup> Department of Semiconductor Engineering, POSTECH	
FA1-B-5 10:30-10:45	Shrinking Contact Hole Patterns by Resist Flow Process and Block Copolymer Technique: Simulation Study Sang-Kon Kim The Faculty of Liberal Arts, Hongik University	



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### O. System LSI Design 분과

[FB1-0] System LSI Design

#### 좌장: 유호영 교수(충남대학교), 정준원 교수(숙명여자대학교)

초청발표 FB1-O-1 09:00-09:30	A Key Building Block of Al Accelerator: In-memory Computing Macros Dong-Jin Chang Chungnam National University	
FB1-O-2 09:30-09:45	Efficient Hardware Implementation of a Non-Linear ActivationFunction ApproximationChanWoo Song, JoonSeok Kim, KyuMin Cho, and SeokHyung KangDepartment of Electrical Engineering, POSTECH	
FB1-O-3 09:45-10:00	Space-Time Transformation을 이용한 Systolic Tensor Array 분석 이동훈, 박지호, 유호영 충남대학교 전자공학과	
초청발표 FB1-O-4 10:00-10:30	Application of Machine Learning for Embedded Memory Circuit Design & Characterization Hanwool Jeong <sup>1,2</sup> <sup>1</sup> 광운대학교, <sup>2</sup> 주식회사 아티크론	
FB1-O-5 10:30-10:45	Programmable ALPG Architecture for High-Speed DRAM Testing Saeyeon Kim, Sunyoung Park, Seoyeon Park, Eunkyung Ham, and Ji-Hoon Kim Department of Electronic and Electrical Engineering, Ewha Womans University	



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### J. Nano-Science & Technology 분과

[FC1-J] 2D Electronics

#### 좌장: 김태욱 교수(전북대학교)

초청발표 FC1-J-1 09:00-09:30	2D Materials beyond the Limit of 3D Bulk Semiconductors Hyesung Park <sup>1,2</sup> <sup>1</sup> Department of Integrative Energy Engineering, Korea University, <sup>2</sup> Ku-Kist Graduate School of Converging Science and Technology, Korea University
FC1-J-2 09:30-09:45	Monolayer MoS <sub>2</sub> Barristor with Covalently Bonded Semi-metal Contact Dong-Yeong Kim <sup>1,2</sup> , Min-Yeong Choi <sup>1,2</sup> , Gun Woo Yoo <sup>1,2</sup> , Ju-Hyun Jung <sup>1,2</sup> , Gunho Moon <sup>1,3</sup> , Moon-Ho Jo <sup>1,3</sup> , and Cheol-Joo kim <sup>1,2</sup> <sup>1</sup> Center for Van der Waals Quantum Solids, IBS, <sup>2</sup> Departmet of Chemical Engineering, POSTECH, <sup>3</sup> Department of Materials Science and Engineering, POSTECH
FC1-J-3 09:45-10:00	AnomalousTemperatureDependenceofCurrent-VoltageCharacteristicsObserved in Graphene/n-Si(100)JunctionJiwan Kim <sup>1</sup> , Hoon Hahn Yoon <sup>2</sup> , Wonho Song <sup>3</sup> , Junhyung Kim <sup>4</sup> , Sungchul Jung <sup>5</sup> ,Eunseok Hyun <sup>1</sup> , and Kibog Park <sup>1,6</sup> <sup>1</sup> Department of Physics, UNIST, <sup>2</sup> School of Electrical Engineering and ComputerScience, GIST, <sup>3</sup> LGDisplay, <sup>4</sup> Terrestrial & Non-Terrestrial IntegratedTelecommunicationsResearch Laboratory, ETRI, <sup>5</sup> SK hynix, <sup>6</sup> Department ofElectrical Engineering, UNIST
초청발표 FC1-J-4 10:00-10:30	Improving the Graphene Conductivity: Exploring Doping Techniques Sukang Bae Functional Composite Materials Research Center, KIST
FC1-J-5 10:30-10:45	Enhanced Photocurrent Generation in Transition Metal Dichalcogenide Heterostructures under Optical Pulse Illumination Jung Woo Lee, Hyeon Sik Jang, Bhishma Pandit, Joung Woo Bong, Ki Hyun Kim, Hag Youl Bae, and Keun Heo School of Semiconductor Science & Technology, Jeonbuk National University



2024년 1월 26일(금), 09:00-10:45 Room D(104),1층

F. Silicon and Group-IV Devices and Integration Technology 분과 [FD1-F] Advanced Integration Technology

#### 좌장: 백명현 교수(강릉원주대학교), 우성윤 교수(경북대학교)

FD1-F-1 09:00-09:15	Heterogeneous 3D Vertical Inverter of MoS <sub>2</sub> nFET on Si pMOSFET Using Sequential Fabrication Process Boncheol Ku <sup>1</sup> , Shanmukh Kutagulla <sup>2</sup> , Deji Akinwande <sup>2</sup> , and Changhwan Choi <sup>1</sup> <sup>1</sup> Division of Materials Science and Engineering, Hanyang University, <sup>2</sup> The Department of Electrical and Computer Engineering, The University of Texas at Austin
FD1-F-2 09:15-09:30	Impact of Low-temperature Deuterium Annealing for Poly-Si Channel Thin-Film Transistors Tae-Hyun Kil, Ju-Won Yeon, Hyo-Jun Park, and Jun-Young Park Chungbuk National University
FD1-F-3 09:30-09:45	그린 레이저를 이용한 모놀리식 3D 소자 제작 공정에서 상부 게이트 버퍼층 삽입을 통한 MOSFET 성능 개선 박영근, 정재중, 김희태, 김성호, 김동빈, 추준홍, 강창연, 조병진 한국과학기술원 전기 및 전자공학부
FD1-F-4 09:45-10:00	Simulation of Monolithic CFET Using In-house TCAD Process Emulator Seung-Woo Jung, In Ki Kim, Kwang-Woon Lee, and Sung-Min Hong School of Electrical Engineering and Computer Science, GIST
FD1-F-5 10:00-10:15	Numerical Simulation of Bottom Dielectric Isolated (BDI) Forksheet Field Effect Transistor (FSFET) with In-House TCAD Process Emulator and Device Simulator In Ki Kim and Sung-Min Hong School of Electrical Engineering and Computer Science, Gwangju Institute of Science and Technology
FD1-F-6 10:15-10:30	Monolithic 3-dimensional Static Random Access Memory Array Cell Consisting of Feedback Field-effect Transistor for Memory System Jong Hyeok Oh and Yun Seop Yu Major of ICT & Robotics Eng., Hankyong National University

FD1-F-7 10:30-10:45	Thickness Scaling of Ferroelectric $HfZrO_2$ and Its Reliability on
	Germanium Substrate
	Jai-Youn Jeong <sup>1,2</sup> , Changhwan Shin <sup>2</sup> , and Jae-Hoon Han <sup>1</sup>
	<sup>1</sup> Center for Opto-electronic Materials and Devices, KIST, <sup>2</sup> Device and Circuit
	Laboratory, Korea University



2024년 1월 26일(금), 09:00-10:45 Room E(105),1층

#### N. VLSI CAD 분과

#### [FE1-N] VLSI CAD to Future Technologies

#### 좌장: 송대건 교수(경북대학교), 현대준 교수(세종대학교)

FE1-N-1 09:00-09:15	A Novel Design of 8T Ternary SRAM for Low Power Jihyeong Yun and Sunmean Kim School of Electronic and Electrical Engineering, Kyungpook National University
FE1-N-2 09:15-09:30	High-throughput PIM (Processing in-memory) for DRAM Using Bank- level Pipelined Architecture Hyunsoo Lee <sup>1</sup> , Hyundong Lee <sup>1</sup> , Minseung Shin <sup>2</sup> , Gyuri Shin <sup>2</sup> , Sumin Jeon <sup>2</sup> , and Taigon Song <sup>1,2</sup> <sup>1</sup> School of Electronic and Electrical Engineering, Kyungpook National University, <sup>2</sup> School of Electronics Engineering, Kyungpook National University
FE1-N-3 09:30-09:45	Mixed-Vth 셀을 활용한 누설전력 최적화 알고리즘 안진일 <sup>1</sup> , 김경창 <sup>2</sup> , 현대준 <sup>1</sup> <sup>1</sup> 세종대학교, <sup>2</sup> 청주대학교
FE1-N-4 09:45-10:00	A Novel Ternary Flip-Flop for Low Area Overhead Ternary Scan Design Hayeon Lee and Sunmean Kim School of Electronic and Electrical Engineering, Kyungpook National University
FE1-N-5 10:00-10:15	GPHFGCN : General-purpose Computing on High-speed and Fully- optimized GCN Accelerator Minseok Han and Taigon Song School of Electronic and Electrical Engineering, Kyungpook National University
FE1-N-6 10:15-10:30	Automated Bitstream Analysis Method for FPGA Reverse Engineering Mannhee Cho <sup>1</sup> , Dongchan Lee <sup>2</sup> , Sanghyun Lee <sup>2</sup> , Youngmin Kim <sup>2</sup> , and Hyung-Min Lee <sup>1</sup> <sup>1</sup> Korea University, <sup>2</sup> Hongik University
FE1-N-7 10:30-10:45	<b>타이밍 제약조건을 고려한 전력분배망 최적화</b> 송정식, 오제영, 현대준 세종대학교 반도체시스템공학과



2024년 1월 26일(금), 09:00-10:45 Room F(106),1층

I. MEMS & Sensor Systems 분과

[FF1-I] Recent Advances in MEMS

#### 좌장: 박윤석 교수(경희대학교), 유재영 교수(성균관대학교)

초청발표 FF1-I-1 09:00-09:30	3D Electrode-Based MEMS Sensors for Biomanufacturing and Biomedical Applications Hyun Soo Kim Kwangwoon University
초청발표 FF1-I-2 09:30-10:00	Photonic FPGA on Silicon Photonic MEMS Sangyoon Han and Min Gi Lim DGIST
FF1-I-3 10:00-10:15	Efficiency Improvement of Ternary Organic Photovoltaic for All-day Operation under Various Light Sources Se Lim Han <sup>1</sup> , Hyojeong Choi <sup>1</sup> , Joo Yeong Kim <sup>2</sup> , Swarup Biswas <sup>1</sup> , and Hyeok Kim <sup>1</sup> <sup>1</sup> School of Electrical and Computer Engineering, University of Seoul, <sup>2</sup> Department of Intelligent Semiconductor Engineering, University of Seoul
FF1-I-4 10:15-10:30	Transfer Technology for Integrating High-Quality Single Crystal Relaxor-Ferroelectric Oxide on Flexible Si Min-Seok Kim <sup>1,2</sup> , Ruiguang Ning <sup>1</sup> , Ho Won Jang <sup>2</sup> , and Seung-Hyub Baek <sup>1</sup> <sup>1</sup> Electronic Materials Research Center, KIST, <sup>2</sup> Department of Materials Science and Engineering, Research Institute of Advanced Materials, Seoul National University
FF1-I-5 10:30-10:45	Metal-Oxide Semiconductors for Chemiresistive-Type Gas SensorsOperating at Room TemperatureSang-Joon Park and Tae-Jun HaDepartment of Electronic Materials Engineering, Kwangwoon University

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2024년 1월 26일(금), 09:00-10:45 Room G(201),2층

## K. Memory (Design & Process Technology) 분과

## [FG1-K] Process and Modeling of Memory

### 좌장: 성석강 마스터(삼성전자), 김시준 교수(강원대학교)

+ + uu =	Device Simulation of Phase-change and Resistive Memories by
초청발표	Modeling Mesoscale Behaviors of Active Materials
FG1-K-1	Dongmyung Jung, Chanhoo Park, Yechan Kim, Hwanwook Lee, Sagar Khot, and
09:00-09:30	Yongwoo Kwon
	Hongik University
	Analysis of Conduction Mechanism and Stress-induced Dielectric
	Leakage Current in 1x-nm DRAM Cell Capacitor for Cryogenic Memory
FG1-K-2	Operation
09:30-09:45	Soohong Eo <sup>1</sup> , Sangwon Lee <sup>1</sup> , Jingyu Park <sup>1</sup> , Seonhaeng Lee <sup>2</sup> , and Dae Hwan Kim <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> Memory Division, Samsung
	Electronics Co., Ltd.
	Realization of Ultra-Low Leakage Current (~10 <sup>-18</sup> A/µm) in CVD Grown
	Monolayer MoS <sub>2</sub> 1T1C DRAM Using Semimetal Bismuth Contact
FG1-K-3	Jisoo Seok <sup>1</sup> , Jae Eun Seo <sup>1</sup> , and Jiwon Chang <sup>1, 2</sup>
09:45-10:00	<sup>1</sup> Department of Materials Science and Engineering, Yonsei University, <sup>2</sup> Department
	of System Semiconductor Engineering, Yonsei University
	3D Stackable Vertical-Sensing Electrochemical Random-Access
	Memory Using AP-PECVD-Grown WS <sub>2</sub> Electrode for Neuromorphic
FG1-K-4	Application Kyumin Lee <sup>1</sup> , Seungkwon Hwang <sup>1,2</sup> , Dongmin Kim <sup>1</sup> , Jongwon Yoon <sup>2</sup> , Jung-Dae
10:00-10:15	Kwon <sup>2</sup> , Yonghun Kim <sup>2</sup> , and Hyunsang Hwang <sup>1</sup>
	<sup>1</sup> Center for Single Atom-based Semiconductor Device and the Department of
	Materials Science and Engineering, POSTECH, <sup>2</sup> Department of Energy and Electronic Materials, Nanosurface Materials Division, KIMS
	Modeling the Valence Change Mechanism and Drift Behavior of
	Oxygen Vacancies in HfO2-Based Interlayer Memristor: A Simulation
FG1-K-5	Approach
10:15-10:30	Eun Young Kim, Juseong Park, Woojoon Park, Woon Hyung Cheong, and Kyung
	Min Kim
	KAIST

	Investigation of Hot Carrier Degradation of 1x-nm DRAM Peripheral
	PMOS Transistors for Cryogenic Memory Applications
FG1-K-6	Ha Young Bang <sup>1</sup> , Hee Jun Lee <sup>1</sup> , Jingyu Park <sup>1</sup> , Seonhaeng Lee <sup>2</sup> , and Dae Hwan
10:30-10:45	Kim <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> Memory Division, Samsung
	Electronics Company, Ltd.

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 26일(금), 09:00-10:45 Room H(203),2층

U. Bio-Medical 분과

[FH1-U] Advanced Biomedical Integrated Circuits and Systems

좌장: 이정협 교수(DGIST), 송민영 교수(DGIST)

초청발표 FH1-U-1 09:00-09:30	An Impedance-measurement IC Achieving Wide Frequency Range and High Throughput for Real-time Biomedical Applications Soon-Jae Kweon The Catholic University of Korea
초청발표 FH1-U-2 09:30-10:00	CMOS Integrated Circuits for High-density Multi-functional Neural Interface Changhyuk Lee <sup>1,2</sup> <sup>1</sup> Brain Science Institute, KIST, <sup>2</sup> Institute for Conversions, Sungkyunkwan University , Sungkyunkwan University
FH1-U-3 10:00-10:15	Wireless System Miniaturization Solutions for Ingestible Sensors Chansoo Park and Minyoung Song DGIST
FH1-U-4 10:15-10:30	A Fully Integrated Wireless Stimulator SoC for Addressable Cortical Microimplant Chae-Eun Lee <sup>1</sup> , Joonyoung Lim <sup>2</sup> , and Yoon-kyu Song <sup>2</sup> <sup>1</sup> Department of Transdisciplinary Studies, Seoul National University, <sup>2</sup> Department of Applied Bioengineering, Seoul National University
FH1-U-5 10:30-10:45	A 2 <sup>nd</sup> -Order $\Delta^2$ - $\Delta\Sigma$ Modulation Based Current Sensing Front-End in Energy and Area Efficient form Factor with Dual PWM Current DAC Jee-Ho Park, Ji-Hyoung Cha, and Seong-Jin Kim UNIST



2024년 1월 26일(금), 09:00-10:45 Room I(203),2층

#### D. Thin Film Process Technology 분과

[FI1-D] Atomic Layer Deposition - I

#### 좌장: 엄태용 선임(한국화학연구원), 송봉근 교수(홍익대학교)

	Pt Thin Films by Atomic Layer Deposition Using Dimethyl(N,N-
초청발표	Dimethyl-3-Buten-1-Amine-N) Platinum and $O_2$ Reactant towards
FI1-D-1	
09:00-09:30	Semiconductor Application Woo-Jae Lee
09:00-09:30	
	<sup>1</sup> Department of Nanotechnology Engineering, Pukyong National University
	Growth of Rutile c-axis Oriented TiO <sub>2</sub> Thin-films with Ultralow
FI1-D-2	Equivalent Oxide Thickness and Leakage Currents
09:30-09:45	Taikyu Kim <sup>1</sup> , Jihoon Jeon <sup>1,2</sup> , Myungsu Jang <sup>1,2</sup> , and Seong Keun Kim <sup>1,2</sup>
	<sup>1</sup> Electronic Materials Research Center, KIST, <sup>2</sup> KU-KIST Graduate School of
	Converging Science and Technology, Korea University
	Improving Performance of $TiO_2/ZrO_2/TiO_2$ Laminated Capacitor by
	Layer-by-layer Phase Control Using Atomic Layer Annealing
	Geongu Han <sup>1</sup> , Kyoungjae Ju <sup>2</sup> , Chanwook Choi <sup>2</sup> , Hyong June Kim <sup>3</sup> , and
FI1-D-3	Jihwan An <sup>2,3</sup>
09:45-10:00	<sup>1</sup> Department of Manufacturing Systems and Design Engineering, Seoul National
	University of Science and Technology, <sup>2</sup> Department of Mechanical Engineering,
	Pohang University of Science and Technology, <sup>3</sup> Institute of Energy and
	Environment, Seoul National University of Science and Technology
	The Effect of Process Pressure on Improving Resistivity of Ru Thin
FI1-D-4	Films Deposited by Atomic Layer Deposition
10:00-10:15	Na-Gyeong Kang, Min-Ji Ha, and Ji-Hoon Ahn
	Department of Materials Science and Chemical Engineering, Hanyang University
FI1-D-5 10:15-10:30	Thermal Atomic Layer Deposition of Ru-incorporated MoCx Films as
	Cu Diffusion Barrier and Seed Layer
	Ji Sang Ahn and Jeong Hwan Han
	Department of Materials Science and Engineering, Seoul National University of
	Science and Technology

	MoO <sub>2</sub> Film Fabrication via Atomic Layer Deposition with Mo(IV)
FI1-D-6	Precursor and Oxygen and Ozone Reactants for DRAM Applications
10:30-10:40	Ara Yoon, Hae Lin Yang, Sanghoon Lee, and Jin-Seong Park
	Division of Materials Science and Engineering, Hanyang University



2024년 1월 26일(금), 09:00-10:45 Room J(204),2층

## A. Interconnect & Package 분과

[FJ1-A] Advanced Packaging II

### 좌장: 김주영 교수(울산과학기술원), 안상훈 수석(삼성전자)

	Electrochemical Study on Better Controllability of Cu Pad Topography
	in Cu/Ti CMP
FJ1-A-1	Seonwoo Go <sup>1</sup> , Yoonji Ra <sup>1</sup> , Jenasree Hazarika <sup>1</sup> , Jum-Yong Park <sup>2</sup> , Un-Byoung Kang <sup>2</sup> ,
09:00-09:15	Tae-Gon Kim <sup>1</sup> , and Jin-Goo Park <sup>1</sup>
	<sup>1</sup> Department of Materials Science and Chemical Engineering, Hanyang University
	ERICA, <sup>2</sup> AVP Process Development Team, Samsung Electronics Co., Ltd.
	Optimization of Chemical Mechanical Polishing (CMP) for Die-to-
FJ1-A-2	Wafer Hybrid Bonding and the Impact of the SiCN Dielectric Layer
09:15-09:30	Yeon Ju Kim, Sang Woo Park, Min Seong Jung, Ji Hun Kim, and Jong Kyung Park
09.15-09.50	Department of Semiconductor Engineering, Seoul National University of Science
	and Technology
	3차원 반도체 패키지를 위한 저온 Cu-Cu 접합용 CuAg 합금 소재 및 신뢰
FJ1-A-3	성 평가
09:30-09:45	이승혁, 전주원, 마지수, 이용규, 김병준
	한국공학대학교 신소재공학과
	Ar Carrier Gas SiN Film Deposition Process Optimization for WLPKG
FJ1-A-4	Chip Warpage Control
09:45-10:00	Intae Whoang, Byung Yoon Lim, Jin Pyung Kim, Kijun Bang, and Seunghee Jo
	SK hynix
	The Impact of Surface Treatment on SiO <sub>2</sub> Bonding for Cu/SiO <sub>2</sub> Hybrid
	Bonding
FJ1-A-5	Injoo Kim <sup>1</sup> , Siye Lee <sup>2</sup> , Wookyung Lee <sup>2</sup> , and Sungdong Kim <sup>2</sup>
10:00-10:15	<sup>1</sup> Department of Mechanical Design and Robot Engineering, Seoul National
	University of Science and Technology, <sup>2</sup> Department of Mechanical System Design
	Engineering, Seoul National University of Science and Technology
	Machine Learning-Based MI Image Classification for A.I
FJ1-A-6	Semiconductor Production
10:15-10:30	Sung Hyun Yoon and Sang Yup Lee
	SK hynix

FJ1-A-7 10:30-10:45	Study on the Chemical Durability and Defect Reduction Effects of
	Ceramic-Based CVD CMP Conditioners
	Yeon-Je Gye <sup>1</sup> , Joo-Han Lee <sup>2</sup> , Sun-Gyu Park <sup>2</sup> , Yu-Jeong Jin <sup>2</sup> , Jin-Goo Park <sup>1</sup> , and
	Tae-Gon Kim <sup>1</sup>
	<sup>1</sup> Department of Materials Science and Chemical Engineering, Hanyang University
	ERICA, <sup>2</sup> Technical Development Electronics BU, EHWA DIAMOND INDUSTRIAL CO.
	LTD.

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2024년 1월 26일(금), 09:00-10:45 Room K(205),2층

G. Device & Process Modeling, Simulation and Reliability 분과 [FK1-G] Device Characterization & Modeling I

### 좌장: 우지용 교수(경북대학교), 김성호 교수(세종대학교)

초청발표 FK1-G-1	Physical Modeling and Evaluation of 3D Memory: Interlayer Guarding
	Effects
	Jo-hak Jeong <sup>1</sup> , Dongkyu Lee <sup>1</sup> , Jin-Taek Lee <sup>1</sup> , Ho Sung Lee <sup>1</sup> , Sang Jun Hwang <sup>1</sup> , Krishna Moorthy Ponnusamy <sup>1,2</sup> , Hyun-Sik Jang <sup>1</sup> , S. Chandramohan <sup>2</sup> , and Keun Heo <sup>1</sup>
09:00-09:30	<sup>1</sup> School of semiconductor science & technology, Jeonbuk National University,
	<sup>2</sup> Department of Physics and Nanotechnology, SRM Institute of Science and
	Technology
	Carrier Transport in In <sub>0.8</sub> Ga <sub>0.2</sub> As HEMTs at Cryogenic Temperature from
FK1-G-2	the Transconductance Modeling Technique in Saturation
09:30-09:45	Min-Seo Yu <sup>1</sup> , Ji-Hoon Yoo <sup>1</sup> , In-Geun Lee <sup>1</sup> , Jae-Hak Lee <sup>1</sup> , Kyounghoon Yang <sup>2</sup> , and
00.00 00.10	Dae-Hyun Kim <sup>1</sup>
	<sup>1</sup> Kyungpook National University, <sup>2</sup> KAIST
	Extraction of Individual Contact Resistance and Threshold Voltage in
	Carbon Nanotube Thin-film Transistors
FK1-G-3	Jun-Ho Jang <sup>1</sup> , Hanbin Lee <sup>1</sup> , Jeonghee Ko <sup>1</sup> , Yulim An <sup>1</sup> , Hyo-In Yang <sup>1</sup> , GyeongSu
09:45-10:00	Min <sup>1</sup> , So Jeong Park <sup>1</sup> , Jeong Yeon Im <sup>1</sup> , Dong Myong Kim <sup>1</sup> , Dae Hwan Kim <sup>1</sup> , Jong-
	Ho Bae <sup>1</sup> , Min-Ho Kang <sup>2</sup> , and Sung-Jin Choi <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> Department of Nano- process, NNFC
	Virtual-Source Based Modeling of Charge-dependent Source
	Resistance and Drain Current of In <sub>x</sub> Ga <sub>1-x</sub> As MBCFETs
FK1-G-4	Su-Min Choi <sup>1</sup> , Ji-Hoon Yoo <sup>1</sup> , Hyeon-Bhin Jo <sup>1</sup> , In-Geun Lee <sup>1</sup> , Hyuk-Min Kwon <sup>2</sup> ,
10:00-10:15	Takuya Tsutsumi <sup>3</sup> , Hiroki Sugiyama <sup>3</sup> , Hideaki Matsuzaki <sup>3</sup> , Jae-Hak Lee <sup>1</sup> , and Dae-
10.00 10.10	Hyun Kim <sup>1</sup>
	<sup>1</sup> Kyungpook National University, <sup>2</sup> Polytechnics, <sup>3</sup> NTT Co.
	Experimental Demonstration of Tunable Synchronization in Coupled
FK1-G-5	$NbO_x$ Artificial Neuron Systems for Neuromorphic Pattern Recognition
10:15-10:30	Hyun Wook Kim, Eunryeong Hong, Nayeon Kim, Seonuk Jeon, and Jiyong Woo
	School of Electronic and Electrical Engineering, Kyungpook National University

FK1-G-6	Investigating Process-Dependent Variations in Amorphous IGZO TFTs
	for 2T-DRAM Application through Monochromatic Photonic C-V
	Analysis
10:30-10:45	Hyunwook Jeong, Junseong Park, Ha-Neul Lee, Yubin Choi, Sung-Jin Choi, Dong
	Myong Kim, Dae Hwan Kim, and Jong-Ho Bae
	School of Electrical Engineering, Kookmin University

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 26일(금), 09:00-10:45 Room L(206),2층

Q. Metrology, Inspection, Analysis, and Yield Enhancement 분과 [FL1-Q] Metrology, Inspection, and Yield Enhancement II

좌장: 강상우 소장(한국표준과학연구원), 정용우 TL(SK 하이닉스)

초청발표 FL1-Q-1 09:00-09:30	반도체 계측 공정에서 영상 처리의 활용 이성일 DRAM Metrology Technology Team, Manufacturing Technology, SK hynix
초청발표 FL1-Q-2 09:30-10:00	A Zerogap Strain Sensor Mahsa Haddadi Moghaddam <sup>1,2</sup> and Dai-Sik Kim <sup>1,2,3,4</sup> <sup>1</sup> Department of Physics, UNIST, <sup>2</sup> Quantum Photonics Institute, UNIST, <sup>3</sup> Center for Angstrom Scale Electromagnetism, UNIST, <sup>4</sup> Department of Physics and Astronomy, Seoul National University
FL1-Q-3 10:00-10:15	Advancing Semiconductor Characterization: Dual Rotating Polarizers Ellipsometry Junho Choi, Jongkyoon Park, Sukhyun Choi, Yong Jai Cho, and Chegal Won Advanced Instrumentation Institute, KRISS
FL1-Q-4 10:15-10:30	AFM을 이용한 EUV Photoresist 프로파일 모니터링 김해리, 권광민, 최규진, 김규영 기반기술센터, 선행 Inspection 기술, SK hynix
FL1-Q-5 10:30-10:45	In-situ Monitoring of Contaminant Particles Generated during PECVD Process Using a Particle Beam Mass Spectrometer Seungjae Lee <sup>1</sup> , Junggil Na <sup>2</sup> , Kyunghwan Jung <sup>2</sup> , and Taesung Kim <sup>1,3</sup> <sup>1</sup> Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> JJ CNS, <sup>3</sup> SKKU Advanced Institute of Nano technology (SAINT), Sungkyunkwan University



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## B. Patterning (Lithography & Etch Technology) 분과

[FA2-B] Lithography and photoresist II

좌장: 이상설 박사(POSTECH), 김진곤 박사(SKMP)

초청발표 FA2-B-1 13:45-14:15	Hybrid Multilayer EUV Dry Photoresist for 1.5 nm Technology Node Myung Mo Sung Hanyang University
FA2-B-2 14:15-14:30	Single EUV Patterning Margin Improvement Minkwon Choi, Hyejun Jin, Jeonghoon Ahn, and Jongho Lee Foundry Business, Samsung Electronics Co., Ltd.
FA2-B-3 14:30-14:45	EUV 펠리클의 Emissivity 에 대한 다층 Emission 구조의 영향 연구 강영우 <sup>1,2</sup> , 김하늘 <sup>1,2</sup> , 김원진 <sup>1,2</sup> , 김정연 <sup>1,2</sup> , 박영욱 <sup>1,2</sup> , 안진호 <sup>1,2</sup> <sup>1</sup> 한양대학교 신소재공학과, <sup>2</sup> EUV-IUCC
FA2-B-4 14:45-15:00	Fizeau Interferometry 를 이용한 EUV Attenuated Phase Shift Mask 평 가 기술 연구 이동기 <sup>1,3</sup> , 문승찬 <sup>2,3</sup> , 홍준호 <sup>1,3</sup> , 안진호 <sup>1,2,3</sup> <sup>1</sup> 한양대학교 신소재공학과, <sup>2</sup> 한양대학교 나노반도체공학과, <sup>3</sup> EUV-IUCC
초청발표 FA2-B-5 15:00-15:30	불소화 주석산화물 극자외선 레지스트 개발 이진균 <sup>1</sup> , 구예진 <sup>1</sup> , 안형주 <sup>1</sup> , 김지호 <sup>2</sup> , 이상설 <sup>2</sup> , 이서현 <sup>3</sup> , 정병준 <sup>3</sup> , 고차원 <sup>4</sup> , 니시츠네히로 <sup>4</sup> , 김현우 <sup>4</sup> <sup>1</sup> 인하대학교 고분자공학과, <sup>2</sup> 포항공대 가속기연구소, <sup>3</sup> 서울시립대학교 신소재공학과, <sup>4</sup> Samsung Electronics Co., Ltd.

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2024년 1월 26일(금), 13:45-15:30 Room B(102),1층

## H. Display and Imaging Technologies 분과

[FB2-H] Display and Imaging Technologies IV

좌장: 전우진 교수(경희대학교)

FB2-H-1 13:45-14:00	Development of High-Performance In <sub>2</sub> O <sub>3</sub> -TFTs Using Atmospheric
	Pressure Spatial ALD toward High Throughput in Flexible Device
	Industry
	Chi-Hoon Lee, Kwang Su Yoo, Dong-Gyu Kim, and Jin-Seong Park
	Division of Materials Science and Engineering, Hanyang University
	Improvement in Negative-Bias-Illumination-Stress Stability in Vertical
FB2-H-2	TFTs Using ALD-IGZO Bilayer Channel Configuration
14:00-14:15	Ji-Won Kang <sup>1</sup> , Yeong-Ha Kwon <sup>2</sup> , Nak-Jin Seong <sup>2</sup> , Kyu-Jeong Choi <sup>2</sup> , Chi-Sun
14.00 14.10	Hwang <sup>3</sup> , Jong-Heon Yang <sup>3</sup> , and Sung-Min Yoon <sup>1</sup>
	<sup>1</sup> Kyung Hee University, Korea, <sup>2</sup> NCD Co. Ltd, <sup>3</sup> ETRI
	Enhancing Performance of Delta Conductance (Delta-C)
FB2-H-3	Characteristics Utilizing Heterojunction Structure for Multi-Valued
14:15-14:30	Logic Application
14.10 14.00	Junho Lee, Chanwoo Jeong, and Jaekyoung Jeong
	Department of Electronic Engineering, Hanyang University
FB2-H-4	Eco-friendly Low Operation Voltage Organic Thin Film Transistors
14:30-14:45	MiRiNae Lee <sup>1</sup> , Min Jong Lee <sup>2</sup> , Swarup Biswas <sup>1</sup> , Jae Won Shim <sup>2</sup> , and Hyeok Kim <sup>1</sup>
14.30-14.43	<sup>1</sup> University of Seoul, <sup>2</sup> Korea University
	Mitigating Short-channel Effects for Nanoscale IGZO Transistor by
	Suppressing Oxygen Diffusion into Metal Utilizing Ultrathin Dielectric
FB2-H-5	Barrier
14:45-15:00	Juyoung Yun <sup>1</sup> , Hyuk Park <sup>1</sup> , Dae-Hwan Kang <sup>2,3</sup> , and Yoonyoung Chung <sup>1,2,3</sup>
14.45-15.00	<sup>1</sup> Department of Electrical Engineering, POSTECH, <sup>2</sup> Department of Semiconductor
	Engineering, POSTECH, <sup>3</sup> Center for Semiconductor Technology Convergence,
	POSTECH
FB2-H-6 15:00-15:15	Control of Subthreshold Gate Swing in a-IGZO Transistors through a
	during Plasma-Enhanced Atomic Layer Deposition
	Seong Hun Yoon and Jae Kyeong Jeong
	Department of Display Science and Engineering, Hanyang University

	Reliability Analysis of SU-8 Passivation on Biocompatible Parylene-
FB2-H-7	Based Flexible PBTTT Organic Thin-Film Transistor
15:15-15:30	Ah-Hyun Hong and Dong-Wook Park
	University of Seoul



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### J. Nano-Science & Technology 분과

[FC2-J] Nano Devices

#### 좌장: 공수현 교수(고려대학교), 금현성 교수(연세대학교)

초청발표 FC2-J-1 13:45-14:15	In-Depth Analysis of Structural Effects on Polarization Switching of Amorphous InGaZnOx Ferroelectric Thin-Film Transistor Hyojin Yang, Sejun Park, Sanghyuk Yun, Haesung Kim, Ha Neul Lee, and Jong-Ho Bae School of Electrical Engineering, Kookmin University
FC2-J-2 14:15-14:30	Degradable Injectable and Tissue-conformable Soft MRI-compatible Brain-interfacing Array Kyuha Park <sup>1,2</sup> , Mikyung Shin <sup>1,2</sup> , and Donghee Son <sup>1,2</sup> <sup>1</sup> Center for Neuroscience Imaging Research, IBS, <sup>2</sup> Sungkyunkwan University
FC2-J-3 14:30-14:45	UtilizingtheDynamicBehaviorCharacteristicsofSelf-healingElectrodes asMemory for Skin ElectronicsDuhwan Seong, Hyunjin Jung, and Donghee SonDepartment of Electrical and Computer Engineering, Sungkyunkwan University
FC2-J-4 14:45-15:00	Magnetic Random-access Memory Based Physical Unclonable Functions Jaimin Kang <sup>1</sup> , Donghyeon Han <sup>1</sup> , Daekyu Koh <sup>1</sup> , San Ko <sup>1</sup> , Kyungchul Lee <sup>2</sup> , Chando Park <sup>3</sup> , Jongsun Park <sup>2</sup> , Kab-Jin Kim <sup>1</sup> , Soogil Lee <sup>1</sup> , Jisung Lee <sup>4</sup> , and Byong-Guk Park <sup>1</sup> <sup>1</sup> KAIST, <sup>2</sup> Korea University, <sup>3</sup> Applied Materials, Inc., <sup>4</sup> Hyundai Motor Company
FC2-J-5 15:00-15:15	Ultrathin Skin-attachable TiO <sub>2</sub> Synaptic Array Integrated with an Organic Proximity Sensor for Real-time Finger Gesture Recognition Haein Cho <sup>1</sup> , Inho Lee <sup>2</sup> , Jingon Jang <sup>1</sup> , Jae-hyun Kim <sup>2</sup> , Hanbee Lee <sup>2</sup> , Sungjun Park <sup>2</sup> , and Gunuk Wang <sup>1</sup>

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F. Silicon and Group-IV Devices and Integration Technology 분과 [FD2-F] Advanced Device Characterizations

좌장: 김명수 교수(울산과학기술원), 권지민 교수(울산과학기술원)

FD2-F-1 13:45-14:00	Multivalued Negative Differential Resistance (NDR) ZnO Channel Thin Film Transistor (TFT) Integrated with Ag/HfO <sub>2</sub> Threshold Switching Device Juho Sung <sup>1</sup> and Changhwan Shin <sup>2</sup> <sup>1</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University, <sup>2</sup> School of Electrical Engineering, Korea University
FD2-F-2 14:00-14:15	Investigation of Interface Trap Effect in Feedback Field Effect Transistor Hangwook Jeong, Minseon Park, Junhyeong Lee, and Min-Woo Kwon Department of Electronic Engineering, Gangneung-Wonju National University
FD2-F-3 14:15-14:30	Steep Slope Transistor with Negligible Hysteresis Achieved through Transient Negative Capacitance Sangho Lee, Giuk Kim, Hunbeom Shin, Yunseok Nam, and Sanghun Jeon School of Electrical Engineering, KAIST
FD2-F-4 14:30-14:45	Design and Characterization of a Double-Trench SiC MOSFET with Superb Current Rectification Yu Jin Kang and Seongjae Cho Department of Electronic and Electrical Engineering, Ewha Womans University
FD2-F-5 14:45-15:00	3D Analysis Methodology for Line Edge Roughness in V-NAND Structure Jaehyuk Lim <sup>1</sup> and Changhwan Shin <sup>2</sup> <sup>1</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University, <sup>2</sup> School of Electrical Engineering, Korea University
FD2-F-6 15:00-15:15	Enhancement Thermal Performance of Drain-extended FinFETs for SOC Applications Yeon Sil Yang and Jang Hyun Kim Department of Intelligence Semiconductor Engineering, Ajou University

FD2-F-7 15:15-15:30	Improved Characteristics of Ag/Ni/HfO2-Based Threshold Switching
	Device
	Daeyoung Chu <sup>1,2</sup> , Sanghyun Kang <sup>3</sup> , and Changhwan Shin <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, Korea University, <sup>2</sup> Samsung Electronics Co., Ltd.,
	<sup>3</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University



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E. Compound Semiconductors 분과

[FE2-E] Compound Semiconductor - GaN HEMTs

좌장: 김동현 박사(한국나노기술원)

초청발표 FE2-E-1 13:45-14:15	The GaN HEMT Technology for beyond 5G and Energy Applications June Sik Kwak RFHIC Inc
FE2-E-2 14:15-14:30	L <sub>g</sub> = 50 nm AlGaN/GaN HEMTs on 4-inch SiC with <i>f<sub>max</sub></i> > 300 GHz Wan-Soo Park <sup>1</sup> , Hyo-Jin Kim <sup>1</sup> , Hyeok-Jun Lee <sup>1</sup> , Sang-Kuk Kim <sup>2</sup> , Jacob Yun <sup>2</sup> , Ted Kim <sup>2</sup> , Jae-Hak Lee <sup>1</sup> , Kyounghoon Yang <sup>3</sup> , and Dae-Hyun Kim <sup>1</sup> <sup>1</sup> Kyungpook National University, <sup>2</sup> QSI, <sup>3</sup> KAIST
FE2-E-3 14:30-14:45	Buffer-related Dynamic On-resistance Characteristics in AlGaN/GaN- on-Si Structures Hyun-Seop Kim Kunsan National University
FE2-E-4 14:45-15:00	Thermal Management of GaN HEMTs through Electro-Thermal Modeling Changhwan Song <sup>1</sup> , Sukwon Choi <sup>2</sup> , and Jungwan Cho <sup>1</sup> <sup>1</sup> School of Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> Department of Mechanical Engineering, The Pennsylvania State University
FE2-E-5 15:00-15:15	Characterization of AlGaN/GaN HEMTs on 4-inch SiC Substrate at Cryogenic Temperature Hyeok-Jun Lee <sup>1</sup> , Wan-Soo Park <sup>1</sup> , Hyo-Jin Kim <sup>1</sup> , Jae-Hak Lee <sup>1</sup> , Kyounghoon Yang <sup>2</sup> , and Dae-Hyun Kim <sup>1</sup> <sup>1</sup> Kyungpook National University, <sup>2</sup> KAIST
FE2-E-6 15:15-15:30	p-GaN/p-AlGaN/AlGaN/GaN Heterojunction Field-effect Transistor with High Threshold Voltage Dong Guk Kim, Jun Hyeok Yim, Min Gi Jeong, Min Kuen Lee, and Ho Young Cha School of Electronic and Electrical Engineering, Hongik University



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### C. Material Growth & Characterization 분과

[FF2-C] Materials synthesis by design

좌장: 김태헌 교수(울산대학교)

초청발표 FF2-C-1 13:45-14:15	Study on Oxide Materials with Combinatorial Methods Seunghun Lee Department of Physics, Pukyong National University
FF2-C-2 14:15-14:30	Differences in Surface Chemical Behavior and Cleaning Mechanism of Si and SiC Yoonji Ra <sup>1</sup> , Juyeol Lee <sup>1</sup> , Jin-Goo Park <sup>1</sup> , Jooyoung Yang <sup>2</sup> , Tae-Uk Kim <sup>2</sup> , and Tae- Gon Kim <sup>1</sup> <sup>1</sup> Department of Materials Science and Chemical Engineering, Hanyang University ERICA, <sup>2</sup> Cleaning Development Team, SK Siltron Co., Ltd.
FF2-C-3 14:30-14:45	Optimization of CVD Growth Conditions for Uniform WS <sub>2</sub> Thin-film Synthesis on a 4-inch Wafer Using a Chloride Precursor Hye Seong Park <sup>1</sup> , Ta Gyu Ryu <sup>1</sup> , Ha Yeon Choi <sup>1</sup> , Hyuk Min Kwon <sup>2</sup> , and Hi Deok Lee <sup>1</sup> <sup>1</sup> Department of Electronics Engineering, Chungnam National University, <sup>2</sup> Semiconductror Convergence Campus of Korea Polytechnics College
초청발표 FF2-C-4 14:45-15:15	Bottom-up Synthesis of 2D Materials for Future Electronics Seok Joon Yun Department of Semiconductor, University of Ulsan
FF2-C-5 15:15-15:30	그 <b>래핀/N(질소)-극성 질화갈륨(GaN)의 열화학적 안정성과 원격 에피택시</b> 최중훈, 홍영준 세종대학교 나노신소재공학과

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## K. Memory (Design & Process Technology) 분과

[FG2-K] Charge Trap Flash Memory

### 좌장: 우성윤 교수(경북대학교), 정연주 박사(KIST)

FG2-K-1 13:45-14:00	A Fully Logic-compatible High-k Charge Trap Memory for sub-28nm Embedded Non-volatile Memory Technologies Jaehun Lee, Kyongsik Yeom, Jongsung Woo, Hyunik Park, Han-Hyeong Choi, Donghwi Hwang, Minji Seo, Hwanho Ma, Jeadong Jung, Jusang Lee, Juwoon Kim, Youngcheon Jeong, Changmin Jeon, Kangho Lee, and Hyunjo Kim Samsung Foundry, Samsung Electronics Co., Ltd.
FG2-K-2 14:00-14:15	Low-power Split-gate NOR Flash Cell Design and Non-ideality Analysis for Compute-in-memory Chan-Gi Yook, Seung-won Lee, and Wonbo Shim Seoul National University of Science and Technology
FG2-K-3 14:15-14:30	고분자 iCVD 증착 기술을 이용한 불소 도핑에 의한 a-InGaZnO 박막 트랜 지스터 소자 특성 향상 오승현 <sup>1</sup> , 이창현 <sup>2</sup> , 조성행 <sup>3</sup> , 김희태 <sup>1</sup> , 박정익 <sup>2</sup> , 김민주 <sup>4</sup> , 박영근 <sup>1</sup> , 정민규 <sup>5</sup> , 박세준 <sup>5</sup> , 임성 갑 <sup>2</sup> , 조병진 <sup>1</sup> <sup>1</sup> 한국과학기술원 전기 및 전자공학부, <sup>2</sup> 한국과학기술원 신소재공학부, <sup>3</sup> 한국전자통신연구원 플렉시블전자소자연구실, <sup>4</sup> 단국대학교 전자전기공학부, <sup>5</sup> Samsung Electronics Co., Ltd.
FG2-K-4 14:30-14:45	Augmenting the Memory Window of Charge Trap Flash through Sputtering Substrate Bias-Induced Trap Generation Hyunyoung Cho <sup>1</sup> , Seongmin Park <sup>1</sup> , and Yoonyoung Chung <sup>1,2,3</sup> <sup>1</sup> Department of Electrical Engineering, POSTECH, <sup>2</sup> Department of Semiconductor Engineering, POSTECH, <sup>3</sup> Center for Semiconductor Technology Convergence, POSTECH
FG2-K-5 14:45-15:00	Improvement on Program/Erase Performance of Amorphous Indium- gallium-zinc-oxide-Based Charge Trap Memory via TCAD Simulation Gyeongsu Min <sup>1</sup> , Hanbin Lee <sup>1</sup> , Yulim An <sup>1</sup> , Jeonghee Ko <sup>1</sup> , Hyo-In Yang <sup>1</sup> , So Jeong Park <sup>1</sup> , Jun-Ho Jang <sup>1</sup> , Jeong Yeon Im <sup>1</sup> , Dong Myong Kim <sup>1</sup> , Dae Hwan Kim <sup>1</sup> , Jong- Ho Bae <sup>1</sup> , Min-Ho Kang <sup>2</sup> , and Sung-Jin Choi <sup>1</sup> <sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> Department of Nano- process, NNFC

FG2-K-7       15:00-15:15       Investigation of Bias Temperature Instabilities of Peripheral pMOSFET and nMOSFET in CTF-NAND Flash Memories with COP Structure for Cryogenic Memory Applications         Jung Rae Cho <sup>1</sup> , Jingyu Park <sup>1</sup> , Tae Jun Yang <sup>1</sup> , Seonhaeng Lee <sup>2</sup> , and Dae Hwar Kim <sup>1</sup> <sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> Memory Division, Samsung Electronics Co., Ltd.
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### K. Memory (Design & Process Technology) 분과

[FH2-K] Ferroelectric Memory I

#### 좌장: 권용우 교수(홍익대학교), 정성엽 박사(차세대융합기술연구원)

FH2-K-1 13:45-14:00	Effect of Al Dopant Distribution in HfO <sub>2</sub> Layer on Ferroelectric Switching Characteristics Hyoungjin Park <sup>1</sup> , Seonuk Jeon <sup>2</sup> , Hyun Wook Kim <sup>2</sup> , Eunryeong Hong <sup>2</sup> , Nayeon Kim <sup>2</sup> , Yunsur Kim <sup>1</sup> , Hyeonsik Choi <sup>1</sup> , Jiae Jeong <sup>1</sup> , and Jiyong Woo <sup>1,2</sup> <sup>1</sup> School of Electronic Engineering, Kyungpook National University, <sup>2</sup> School of Electronic and Electrical Engineering, Kyungpook National University
FH2-K-2 14:00-14:15	Novel Dual Ferroelectric Stack with Wide-range Tunable Coercive Voltage for High-density 3D FeNAND Applications Jiae Jeong <sup>1</sup> , Nayeon Kim <sup>2</sup> , Hyunwook Kim <sup>2</sup> , Eunryeong Hong <sup>2</sup> , Seonuk Jeon <sup>2</sup> , Yunsur Kim <sup>1</sup> , Hyeonsik Choi <sup>1</sup> , Hyoungjin Park <sup>1</sup> , and Jiyong Woo <sup>1,2</sup> <sup>1</sup> School of Electronic Engineering, Kyungpook National University, <sup>2</sup> School of Electronic and Electrical Engineering, Kyungpook National University
FH2-K-3 14:15-14:30	La2O3 중간층을 이용한 Ferroelectric FET 의 성능 및 내구성 개선 강창연, 추준홍, 김성호, 박영근, 김승훈, 조병진 한국과학기술원 전기 및 전자공학부
FH2-K-4 14:30-14:45	Enhancing Non-Volatile Memory Performance: Dual Ferroelectric Gate Field-Effect Transistors with Recessed Channel Geometry Simin Chen <sup>1</sup> , Dae-Hwan An <sup>2</sup> , Seong Ui An <sup>1</sup> , Tae Hyeon Noh <sup>1</sup> , and Younghyun Kim <sup>1</sup> <sup>1</sup> Department of Photonics and Nanoelectronics, BK21 FOUR ERICA-ACE Center, Hanyang University, <sup>2</sup> Center for Opto-electronic Materials and Devices, KIST
FH2-K-5 14:45-15:00	Demonstration of Programmable Low-Temperature Hf-Based Ferroelectric Amorphous Oxide Semiconductor FET for Emerging Memory Applications Tae Hyeon Noh <sup>1</sup> , Dae-Hwan Ahn <sup>2</sup> , Hyo-Bae Kim <sup>3</sup> , Taewon Jin <sup>1</sup> , Seoung min Park <sup>1</sup> , Seong Ui An <sup>1</sup> , Xinkai Sun <sup>1</sup> , Simin Chen <sup>1</sup> , Ji-Hoon Ahn <sup>3</sup> , and Younghyun Kim <sup>1</sup> <sup>1</sup> Department of Photonics and Nanoelectronics, BK21 FOUR ERICA-ACE Center, Hanyang University, <sup>2</sup> Center for Opto-electronic Materials and Devices, KIST, <sup>3</sup> Department of Materials Science and Chemical Engineering, Hanyang University

FH2-K-6 15:00-15:15	Analysis of Hydrogen Effect on Ferroelectric $(Hf,Zr)O_2$ Thin Films
	during Atomic Layer Deposition Process
	Seongbin Park <sup>1</sup> , Seungbin Lee <sup>1</sup> , Hye Ryeon Park <sup>1</sup> , Jongmug Kang <sup>1</sup> , Juntak Jeong <sup>1</sup> ,
	Yeseo Choi <sup>1</sup> , Jin-Hyun Kim <sup>2</sup> , Minjong Lee <sup>2</sup> , Jiyoung Kim <sup>2</sup> , and Si Joon Kim <sup>1</sup>
	<sup>1</sup> Kangwon National University, <sup>2</sup> The University of Texas at Dallas
	The Effect of Oxygen Vacancy Layer on Memory Performance of
FH2-K-7	Hafnia Ferroelectric Tunnel Junction
15:15-15:30	Junghyeon Hwang, Chaeheon Kim, Hunbeom Shin, and Sanghun Jeon
	School of Electrical Engineering, KAIST
	The Effect of Oxygen Vacancy Layer on Memory Performance of Hafnia Ferroelectric Tunnel Junction Junghyeon Hwang, Chaeheon Kim, Hunbeom Shin, and Sanghun Jeon



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#### D. Thin Film Process Technology 분과

#### [FI2-D] Atomic Layer Deposition - II

#### 좌장: 김성근 책임(한국과학기술연구원), 최병준 교수(서울과학기술대학교)

FI2-D-1 13:45-14:00	Modulation of Atomic Layer Deposition for Improvement of Conformality on High Aspect Ratio Substrates Jiwon Kim <sup>1</sup> , Changbong Yeon <sup>2</sup> , Deok-Hyeon Cho <sup>2</sup> , Jaesun Jung <sup>2</sup> , and Bonggeun Shong <sup>1</sup> <sup>1</sup> Hongik University, <sup>2</sup> Soulbrain
FI2-D-2 14:00-14:15	Theoretical Screening of Tungsten Precursors toward Inherent Area- selective Atomic Layer Deposition of WO <sub>3</sub> between Nitride Substrates Su-Jin Kwon, Junhui Choi, Ju Hyeon Jung, and Bonggeun Shong Chemical Engineering, Hongik University
FI2-D-3 14:15-14:30	Enhanced Deposition Selectivity of High-k Dielectrics by Vapor-Dosed Self-Assembled Monolayer Inhibitors Combined with Selective Lift-Off Jeong-Min Lee and Woo-Hee Kim Department of Materials Science and Chemical Engineering, Hanyang University
FI2-D-4 14:30-14:45	Theoretical Analysis on the Influence of Ge Precursors toward Atomic Layer Deposition of Germanium Tellurides Hyeon Cho and Bonggeun Shong Hongik University
FI2-D-5 14:45-15:00	Growth Characteristics of Plasma-Enhanced Atomic Layer Deposition of SiN <sub>x</sub> by BTBAS and BDEAS with a Very High Frequency Plasma Source Young-Jin Lim <sup>1</sup> , Min-Jeong Rhee <sup>1</sup> , Ngoc Le Trinh <sup>2</sup> , Han-Bo-Ram Lee <sup>2</sup> , and II-Kwon Oh <sup>1</sup> <sup>1</sup> Department of Intelligence Semiconductor Engineering, Ajou University, <sup>2</sup> Department of Materials Science and Engineering, Incheon National University
FI2-D-6 15:00-15:15	Temperature-dependent Surface Reactions in Atomic Layer Deposition of Titanium Nitride Jae Min Jang, Ju Hyeon Jung, and Bonggeun Shong Hongik University

	Theoretical Analysis of Niobium Precursors toward Inherent Area-
FI2-D-7	selective Atomic Layer Deposition between Nitride Substrates
15:15-15:30	Junhui Choi, Miso Kim, and Bonggeun Shong
	Hongik University



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#### D. Thin Film Process Technology 분과

[FJ2-D] Thin Film Transistors - I

#### 좌장: 안지훈 교수(한양대학교), 백인환 교수(인하대학교)

FJ2-D-1 13:45-14:00	Performance Enhancement of In-Ga-Zn-O Vertical-channel TFTs with
	a Channel Length of 40 nm via $Al_2O_3$ Spacer Engineering
	Chae-Eun Oh <sup>1</sup> , Young-Ha Kwon <sup>2</sup> , Nak-Jin Seong <sup>2</sup> , Kyu-Jeong Choi <sup>2</sup> , and Sung-Min
	Yoon <sup>1</sup>
	<sup>1</sup> Kyung Hee University, <sup>2</sup> NCD Co., Ltd.
	Back-End-of-Line Compatible $AI_2O_3$ Passivated p-Type Copper(I) Oxide
FJ2-D-2	Thin Film Transistors with Enhanced Current On/Off Ratio
	Seohyeon Park <sup>1</sup> , Jaewook Yoo <sup>1</sup> , Hyeonjun Song <sup>1</sup> , Soyeon Kim <sup>1</sup> , Hongseung Lee <sup>1</sup> ,
14:00-14:15	Seongbin Lim <sup>1</sup> , Minah Park <sup>1</sup> , Peide D. Ye <sup>2</sup> , and Hagyoul Bae <sup>1</sup>
	<sup>1</sup> Jeonbuk National University, <sup>2</sup> Purdue University
	IGZO 2TOC DRAM with Normally-off Operation Using Interfacial Dipole
	Suwon Seong <sup>1</sup> , Seongmin Park <sup>1</sup> , Taejun Ha <sup>1</sup> , Hyunyoung Cho <sup>1</sup> , Daehwan Kang <sup>2,3</sup> ,
FJ2-D-3	and Yoonyoung Chung <sup>1,2,3</sup>
14:15-14:30	<sup>1</sup> Department of Electrical Engineering, POSTECH, <sup>2</sup> Department of Semiconductor
	Engineering, POSTECH, <sup>3</sup> Center for Semiconductor Technology Convergence,
	POSTECH
	High-performance Graphene-Based Field Effect Transistors Fabricated
	by UV-assisted Atomic Layer Deposition
FJ2-D-4	Geonwoo Park <sup>1</sup> , Jeong Woo Shin <sup>2</sup> , Dohyun Go <sup>3</sup> , and Jihwan An <sup>4</sup>
14:30-14:45	<sup>1</sup> Manufacturing Systems and Design Engineering, SEOULTECH, <sup>2</sup> Department of
	Mechanical Engineering, Nanyang Technological University, <sup>3</sup> Department of
	Chemistry, U.C. San Diego, <sup>4</sup> Department of Mechanical Engineering, POSTECH
	The C-V-Based Investigation of Capacitive Coupling in the Sub-micron
	Amorphous InGaZnO Thin-film Transistors Depending on the Device
FJ2-D-5	Structure, Gate Dielectric Material, and Anneal Temperature
14:45-15:00	Sae Him Jung <sup>1</sup> , Seung Joo Myoung <sup>1</sup> , Donguk Kim <sup>1</sup> , Sangwook Kim <sup>2</sup> , Kwang-Hee
	Lee <sup>2</sup> , Moonil Jung <sup>2</sup> , Narae Han <sup>2</sup> , Jee-Eun Yang <sup>2</sup> , Younjin Jang <sup>2</sup> , and Dae Hwan Kim <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> SAIT

FJ2-D-6 15:00-15:15	Investigating Defects on Channel Surface of IGZO Thin-film Transistors under Ozone Annealing and UV Treatment Myeong Woo Ju <sup>1,2</sup> , Changyong Oh <sup>1,2</sup> , Taehyeon Kim <sup>3</sup> , Min Young Kim <sup>1</sup> , So Hee Park <sup>1</sup> ,Geon Hyeong Lee <sup>1</sup> , and Bo Sung Kim <sup>1,2</sup> <sup>1</sup> Department of Applied Physics, Korea University, <sup>2</sup> E·ICT-Culture·Sports Track,
	Korea University, <sup>3</sup> Memory Diffusion Technology Team, Samsung Electronics Co.,
	Ltd.
FJ2-D-7 15:15-15:30	Rapid Thermal Annealing (RTA) to Recover the Radiation Damage of
	a-IGZO TFTs for Highly Reliable DRAM Cell Transistors
	Minah Park, Jaewook Yoo, Hyeonjun Song, Soyeon Kim, Hongseung Lee, Seongbin
	Lim, Seohyeon Park, Yoon Kyeung Lee, Keun Heo, and Hagyoul Bae
	Jeonbuk National University



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G. Device & Process Modeling, Simulation and Reliability 분과 [FK2-G] TCAD & Compact Modeling

좌장: 최성진 교수(국민대학교), 김현우 교수(건국대학교)

초청발표 FK2-G-1 13:45-14:15	Enhancing AC Degradation Modeling by considering the Degradation Profile Induced by DC Stress in SiON pMOSFETs Yeohyeok Yu Department of Information and Communication Technology Engineering, Jeonju University
FK2-G-2 14:15-14:30	Physical Compact Model of Double-Gate MOSFET with a-IGZO Channel for Cell Array Transistor in 3-Dimensional DRAM Tae-Hyun Park and Ji-Woon Yang Department of Electronics and Information Engineering, Korea University
FK2-G-3 14:30-14:45	Quasi 2-Dimensional Compact Model of Channel-All-Around MOSFETs for 3-Dimensional DRAM Chae-Young Kim and Ji-Woon Yang Department of Electronics and Information Engineering, Korea University
FK2-G-4 14:45-15:00	Intrinsic Delay Optimization on Lateral Source/Drain Growth Profile for NanosheetField-effect Transistor Jae Woog Jung, Hwi Seung Park, and Hyun Woo Kim Department of Electrical and Electronics Engineering, Konkuk University
FK2-G-5 15:00-15:15	Exploring the Impact of Channel Tapered Angle and Number of Channel Stacks in Nanosheet and Forksheet FETs Yonghwan Ahn, Junjong Lee, Jinsu Jeong, Seunghwan Lee, Sanguk Lee and Rock-Hyun Baek Department of Electrical Engineering, POSTECH
FK2-G-6 15:15-15:30	Accelerated Device Simulation of Gate-all-around Nanosheet MOSFETs Using Quasi-1D Model Kwang-Woon Lee and Sung-Min Hong School of Electrical Engineering and Computer Science, GIST

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Q. Metrology, Inspection, Analysis, and Yield Enhancement 분과 [FL2-Q] Metrology, Inspection, and Yield Enhancement III

좌장: 강상우 소장(한국표준과학연구원), 정용우 TL(SK 하이닉스)

FL2-Q-1 13:45-14:00	Wafer Inspection with High-speed Microdeflectometry Manh Nguyen The <sup>1</sup> , Young-Sik Ghim <sup>1,2</sup> , and Hyug-Gyo Rhee <sup>1,2</sup> <sup>1</sup> KRISS, <sup>2</sup> UST
FL2-Q-2 14:00-14:15	FTIR 및 기계학습을 활용한 SiN에 미치는 방사선 영향 분석 Dong-Hyeon Kim and Sung-Uk Zhang Digital Twin Laboratory, Dong-Eui University
FL2-Q-3 14:15-14:30	Strain-enhanced Ion Drift Localization of 2D Van der Waals Ferroelectric Heterojunction via Tip-induced Strain Engineering Jinhyoung Lee <sup>1</sup> , Gunhoo Woo <sup>2,3</sup> , Jinill Cho <sup>1</sup> , Yoonseok Noh <sup>5</sup> , Hyelim Shin <sup>5</sup> , Donghyuk Choi <sup>6</sup> , and Taesung Kim <sup>1,2,3,4,5</sup> <sup>1</sup> School of Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> SKKU Advanced Institute of Nanotechnology, Sungkyunkwan University, <sup>3</sup> Department of Nano Science and Technology, Sungkyunkwan University, <sup>4</sup> Department of Nano Engineering, Sungkyunkwan University,
FL2-Q-4 14:30-14:45	Development of Physical Force-Assisted Wet Cleaning Process for Removing Highly Chemically Resistant Organic Residue Jae-Hyeong Lee <sup>1</sup> , Tae-Yoon Jung <sup>1</sup> , Kyoung-Chae Seo <sup>2</sup> , Byoung-Pil Lee <sup>2</sup> Eun-Jin Kim <sup>2</sup> , Han-Ku Cho <sup>2</sup> , Jin-Goo Park <sup>1</sup> , and Tae-Gon Kim <sup>1</sup> <sup>1</sup> Department of Materials Science and Chemical Engineering, Hanyang University ERICA, <sup>2</sup> FST, Fine Semitech Corp.
FL2-Q-5 14:45-15:00	경화 공정 수율 증대를 위한 다물리기반 경화 해석 및 딥러닝 네트워크 김경빈 <sup>1</sup> , 이은호 <sup>1,2</sup> <sup>1</sup> 성균관대학교 기계공학과, <sup>2</sup> 성균관대학교 지능형 펩테크 융합전공

FL2-Q-6 15:00-15:15	Thermo-reflectance Microscope and Semiconductor Applications Ki Soo Chang <sup>1</sup> , Dong Uk Kim <sup>1</sup> , Chan Bae Jeong <sup>1</sup> , Ilkyu Han <sup>1</sup> , Dong Mok Kim <sup>1</sup> , Seung-Woo Lee <sup>2</sup> , and Byung-Seon Chun <sup>2</sup> <sup>1</sup> Division of Scientific Instrumentation, KBSI, <sup>2</sup> Nanoscope Systems, Inc.
FL2-Q-7 15:15-15:30	Anomaly Classification for Multivariate Time-Series with Noisy Labels: A Semi-Supervised Approach Jun Hui Lee and PooGyeon Park Department of Electrical Engineering, POSTECH



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#### R. Semiconductor Software 분과

#### [FA3-R] Semiconductor Software

#### 좌장: 강동현 교수(가천대학교), 김재호 교수(경상국립대학교)

초청발표 FA3-R-1 15:40-16:10	Multi-tenant를 지원하는 Flash Storage 기술 트렌드와 전망 In Hwan Doh Samsung Electronics Co., Ltd.
FA3-R-2 16:10-16:25	Eyana: The SSD Simulator Exploring the Inner Workings of Solid-State Drives Habibur Rahman <sup>1</sup> , Jaeho Kim <sup>1</sup> , and Omar Faroque <sup>2</sup> <sup>1</sup> Department of Al Convergence Engineering, Gyeongsang National University, <sup>2</sup> Department of Computer Science, University of Texas at Austin
FA3-R-3 16:25-16:40	Can Remote Compaction Improve Performance in LSM-KV Store? Honghyeon Yoo, Jeeseob Kim, Seungjae Lee, Hongsu Byun, and Sungyong Park Department of Computer Science and Engineering, Sogang University
FA3-R-4 16:40-16:55	Offloading Erasure Coding to CSD in Hyperledger Fabric Junghyun Ryu <sup>1</sup> , Hongsu Byun <sup>1</sup> , Myungcheol Lee <sup>2</sup> , Jinchun Choi <sup>2</sup> , and Youngjae Kim <sup>1</sup> <sup>1</sup> Sogang University, <sup>2</sup> Smart Data Research Section, ETRI
FA3-R-5 16:55-17:10	Can a Block Cache in LSM-KV Store Accelerates Stateful Query? Dongjae Lee, Yeonwoo Jeong, Sungyong Park Department of Computer Science and Engineering, Sogang University

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H. Display and Imaging Technologies 분과

[FB3-H] Display and Imaging Technologies V

좌장: 권혁인 교수(중앙대학교)

FB3-H-1 15:40-15:55	Partially Transparent Flexible IGZO TFT with PEDOT:PSS Gate and
	Parylene-C Gate Dielectric Yoojeong Ko and Dong-Wook Park University of Seoul
	Extracting Bulk Trap Density of Oxide Semiconductor Thin Films Using
	Space Charge Limited Current
FB3-H-2	Changeon Jin <sup>1</sup> , Taewon Seo <sup>1</sup> , and Yoonyoung Chung <sup>1,2,3</sup>
15:55-16:10	<sup>1</sup> Department of Electrical Engineering, POSTECH, <sup>2</sup> Department of Semiconductor
	Engineering, POSTECH, <sup>3</sup> Center for Semiconductor Technology Convergence, POSTECH
	Fabrication and Applications of a-ITZO Charge-Trapping TFTs Using
FB3-H-3	$AI_2O_3$ and $HfO_2$ in Memory-In-Pixel Display Technology
16:10-16:25	Seoungmin Park <sup>1</sup> , Taehyeon Noh <sup>1</sup> , Youngyeong Lee <sup>2</sup> , and Younghyun Kim <sup>1</sup>
10.10 10.20	<sup>1</sup> Department of Photonics and Nanoelectronics, BK21 FOUR ERICA-ACE Center,
	Hanyang University, <sup>2</sup> HANA Optronic, Inc.
	Controllable, Large Gamut Sensitivity for Stretchable Strain Sensors
FB3-H-4	With One Dimensional Single Walled Carbon Nanotubes
16:25-16:40	Hyeonbin-Jo, Yujin Choi, Taeho Kang, Gyubeen Kim, and Sung Hun Jin
	Department of Electronic Engineering, and I-Nanofab Center, Incheon National University
FB3-H-5	Ambipolar Organic Inverter based on Non-fullerene Acceptor
16:40-16:55	Seungyeon Koh, MiRiNae Lee, HwaPyeong Noh, Swarup Biswas, and Hyeok Kim
10.40-10.55	School of Electrical and Computer Engineering, University of Seoul
	Low-hydrogen SiO <sub>x</sub> N <sub>y</sub> Thin Film via Plasma-enhanced Atomic Layer
FB3-H-6 16:55-17:10	Deposition Using a Hydrogen-free Silicon Precursor and $N_2$ Plasma :
	Growth Mechanism and Dielectric Properties
	Chae-Yeon Park <sup>1</sup> , Hae Lin Yang <sup>1</sup> , Tae-Yeon Kim <sup>1</sup> , Gi-Beom Park <sup>1</sup> , Ara Yoon <sup>1</sup> ,
	Jongryul Park <sup>2</sup> , Taehyeong Kang <sup>2,3</sup> , Yongjoo Park <sup>3</sup> , and Jin-Seong Park <sup>1</sup>
	<sup>1</sup> Division of Materials Science and Engineering, Hanyang University, <sup>2</sup> SK Trichem
	Co., Ltd.

FB3-H-7 17:10-17:25	Copper-lodide Film Formation via Physical Vapor Deposition Method
	and Their Electrical Contact and Sheet Resistance Properties
	Geun Lee, Da Han Lee, Tae Ho Kang, Tae Won Jin, Woo In Kim, and Sung Hun Jin
	Department of Electronic Engineering, and I-Nanofab Center, Incheon National
	University



2024년 1월 26일(금), 15:40-17:25 Room C(104),1층

T. AI 분과

[FC3-T] Artificial Intelligence

좌장: 김병수 센터장(한국전자기술연구원)

초청발표 FC3-T-1 15:40-16:10	Challenges on Efficient Inference of Large Language Models Se Jung Kwon NAVER Cloud
초청발표 FC3-T-2 16:10-16:40	An Efficient Inference Using Synchronization-Aware NAS and CUTLASS GEMM Optimization on Mobile Systems Yongjun Park Yonsei University
FC3-T-3 16:40-16:55	A Real-time 3D Hand Pose Based Control System Using Lightweight Point Cloud Inference on a Mobile GPU Jaehyeon So, Johnny Rhe, and Jong Hwan Ko Department of Electrical and Computer Engineering, Sungkyunkwan University
FC3-T-4 16:55-17:10	Efficient Source-Free Subject Feature Adaptation for Generalizing EEG-Based Motor Imagery Classification Models Chanwook Hwang and Jong Hwan Ko Department of Electrical and Computer Engineering, Sungkyunkwan University
FC3-T-5 17:10-17:25	Column-Major and Input-Stationary Mapping for Efficient In-memory Inference of Depth-Wise Convolutional Layers Juhong Park and Jong Hwan Ko Department of Electrical and Computer Engineering, Sungkyunkwan University



2024년 1월 26일(금), 15:40-17:25 Room D(104),1층

F. Silicon and Group-IV Devices and Integration Technology 분과 [FD3-F] Advanced Device Applications

좌장: 김시현 교수(서강대학교), 우성윤 교수(경북대학교)

FD3-F-1 15:40-15:55	TiO2층이 삽입된 시냅스용 플래시 메모리 소자의 가중치 선형성 개선 연구 이성현, 이왕주, 김진하, 김상훈, 박정우, 박민아, 정순규, 손민균, 서동우 한국전자통신연구원
FD3-F-2 15:55-16:10	CMOS-compatibleRoom-temperatureWaveguide-integratedPhotodetector basedon Ge-on-insulator PhotonicPlatform for Mid-infrared ApplicationsJoonsup Shim, Jinha Lim, Inki Kim, and SangHyeon KimKAIST
FD3-F-3 16:10-16:25	Free-standing Germanium Photonic Crystal Waveguide for Mid- infrared On-chip Gas Sensor Inki Kim, Jinha Lim, Joonsup Shim, and SangHyeon Kim School of Electrical Engineering, KAIST
FD3-F-4 16:25-16:40	An Ultra-low Power 3D DRAM based on SiGe Heterojunction Hyangwoo Kim <sup>1</sup> , Ju Hong Park <sup>2</sup> , and Chang-Ki Baek <sup>2</sup> <sup>1</sup> Future IT Innovation Laboratory, POSTECH, <sup>2</sup> Department of Convergence IT Engineering, POSTECH
FD3-F-5 16:40-16:55	Low-power and Tunable Leaky Integrate-and-Fire Neuron Using Resistive Switching Transistor based on Silicon-Germanium Heterojunction Yijoon Kim, Ju Hong Park, and Chang-Ki Baek Department of Convergence IT Engineering, POSTECH
FD3-F-6 16:55-17:10	Self-rectifying Characteristics by Metal Work Functions at TiO <sub>2</sub> /HfO <sub>2</sub> Multilayer RRAM Chan-Hyeok Nam and Myung-Hyun Baek Gangneung-Wonju National University

FD3-F-7 17:10-17:25	Research on Electrical Characteristics of Neuromorphic Device with
	Pt/Cr/HfO2/Pt/Cr/HfO2/SiO2/Si Gate Stack
	Jeong Mok Yang <sup>1</sup> , So Yeon Jeong <sup>1</sup> , Jae Min Kim <sup>1</sup> , Tae Hwan Koo <sup>1</sup> , Su Hyeon Chae <sup>1</sup> , and Moon Gyu Jang <sup>1,2</sup>
	<sup>1</sup> School of Nano Convergence Technology, Hallym University, <sup>2</sup> Center of Nano Convergence Technology, Hallym University

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2024년 1월 26일(금), 15:40-17:25 Room E(105),1층

E. Compound Semiconductors 분과

[FE3-E] Compound Semiconductor - Modeling & Process

좌장: 이종원 박사(NNFC)

FE3-E-1 15:40-15:55	Investigation on Carrier Transport Properties for AlGaN/GaN HEMTs on SiC from the L <sub>g</sub> Scaling Behavior of Transconductance in Saturation Hyo-Jin Kim <sup>1</sup> , In-Geun Lee <sup>1</sup> , Wan-Soo Park <sup>1</sup> , Hyeok-Jun Lee <sup>1</sup> , Jae-Hak Lee <sup>1</sup> , Kyounghoon Yang <sup>2</sup> , and Dae-Hyun Kim <sup>1</sup> <sup>1</sup> Kyungpook National University, <sup>2</sup> KAIST
FE3-E-2 15:55-16:10	Enhancing Carrier Transport In AlGaN/GaN HEMTs Through Structural Optimization And Transconductance Modeling Hyo-Joung Kim, Walid Amir, Surajit Chakraborty, Hyeon-Cheol Jeong, Myeong- Jun You, and Tae-Woo Kim School of Electrical and Electronic Engineering, University of Ulsan
FE3-E-3 16:10-16:25	Comprehensive Analysis of Self-heating Effects in Multi-finger GaN- on-SiHEMTs Jaeyong Jeong <sup>1</sup> , Sung Joon Choi <sup>1</sup> , Joonsup Shim <sup>1</sup> , Eunjung Kim <sup>1</sup> , Seong Kwang Kim <sup>1</sup> , Bong Ho Kim <sup>1</sup> , Joon Pyo Kim <sup>1</sup> , Yoon Je Suh <sup>1</sup> , Nahyun Rheem <sup>1</sup> , Woo jin Beak <sup>1</sup> , Dae Myeong Geum <sup>2</sup> , Yumin Koh <sup>3</sup> , Donghyun Kim <sup>3</sup> , and Sanghyeon Kim <sup>1</sup> <sup>1</sup> School of Electrical Engineering, KAIST, <sup>2</sup> School of Electronic Engineering, Chungbuk National University, <sup>3</sup> KANC
FE3-E-4 16:25-16:40	The Impact of T-Gate Head Size on Radiation Tolerance in GaN HEMTs Sung-Jae Chang <sup>1</sup> , Dong-Seok Kim <sup>2</sup> , Hyun-Wook Jung <sup>1</sup> , Dohyun Kim <sup>1</sup> , II-Gyu Choi <sup>1</sup> , Youn-Sub Noh <sup>1</sup> , Sang-Heung Lee <sup>1</sup> , Seong-II Kim <sup>1</sup> , Ho-Kyun Ahn <sup>1</sup> , Jong-Won Lim <sup>1</sup> , and Dong-Min Kang <sup>1</sup> <sup>1</sup> Photonic/Wireless Convergence Research Department, ETRI, <sup>2</sup> Korea Multi- Purpose Accelerator Complex, KAERI
FE3-E-5 16:40-16:66	Extraction of Effective Mobility for In <sub>0.8</sub> Ga <sub>0.2</sub> As/In <sub>0.52</sub> Al <sub>0.48</sub> As QW HEMTs at Cryogenic Temperature Sang-Pyeong Son <sup>1</sup> , Ji-Hoon Yoo <sup>1</sup> , Seung-Woo Son <sup>1</sup> , In-Geun Lee <sup>1</sup> , Jae-Hak Lee <sup>1</sup> , Kyounghoon Yang <sup>2</sup> , and Dae-Hyun Kim <sup>1</sup> <sup>1</sup> Kyungpook National University, <sup>2</sup> KAIST

	AlGaN/GaN 이종 접합 트랜지스터의 격리 공정을 위한 이온주입 공정 연구
FE3-E-6	Jun-Hyeok Yim, Seung-Heon Shin, Min-Jeoung Kim, Dong-Ik Oh, Min-Keun Lee,
16:55-17:10	Min-Gi Jeong, and Ho-Young Cha
	School of Electronic and Electrical Engineering, Hongik University
FE3-E-7 17:10-17:25	Next Generation Infrared Detector based on Type-II Superlattice
	Hyun-Woo Jang <sup>1</sup> , Jun-Ho Eom <sup>1</sup> , Byung-Hyuk Kim <sup>1</sup> , Han Jung <sup>1</sup> , Sun Ho Kim <sup>2</sup> , Jun
	Hee Choi <sup>3</sup> , Sang-Sun Yong <sup>4</sup> , and Young Ho Kim <sup>1</sup>
	<sup>1</sup> i3system, Inc., <sup>2</sup> Agency of Defense Development, <sup>3</sup> KRIT, <sup>4</sup> Korea Aerospace
	Research Institute

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 26일(금), 15:40-17:25 Room F(106),1층

I. MEMS & Sensor Systems 분과

[FF3-I] Recent Advances in Sensor Geometry and Materials

좌장: 박윤석 교수(경희대학교)

FF3-I-1 15:40-15:55	Dielectrically-modulated Thyristor Based Biosensor for Enhanced
	Sensitivity
	Chan Heo <sup>1</sup> , Sein Oh <sup>1</sup> , Hyeongyu Kim <sup>1</sup> , Keun Heo <sup>2</sup> , and Kihyun Kim <sup>1</sup>
	<sup>1</sup> Division of Electronic Engineering, Jeonbuk National University, <sup>2</sup> Department of
	Semiconductor Science and Technology, Jeonbuk National University
	Flexible Pressure Sensor with High Performance and Durability based
	on Porous Polymer Thin-Film
FF3-I-2	Sehwan Park <sup>1</sup> , Sanghoon Park <sup>2</sup> , Haechang Lee <sup>3</sup> , Seunghyup Yoo <sup>2</sup> , and Hanul
15:55-16:10	Moon <sup>1</sup>
13.33-10.10	<sup>1</sup> Department of Chemical Engineering (BK21 FOUR Graduate Program) &
	Department of Semiconductors, Dong-A University, <sup>2</sup> School of Electrical
	Engineering, KAIST, <sup>3</sup> Center for Biomaterials, Biomedical Research Institute, KIST
	Hybrid Energy Harvesting System to Improve Power Efficiency of
	Organic Photovoltaics in Indoor Light Sources with Triboelectric
FF3-I-3	Nanogenerator
16:10-16:25	Hyojeong Choi <sup>1</sup> , Selim Han <sup>1</sup> , Jooyeong Kim <sup>2</sup> , Biswas Swarup <sup>1</sup> , and Hyeok kim <sup>1</sup>
	<sup>1</sup> School of Electrical and Computer Engineering, University of Seoul, <sup>2</sup> Department
	of Intelligent Semiconductor Engineering, University of Seoul
	Micro-Electronic Mechanical Switch (MEMS) Based Field-
FF3-I-4	Programmable Photonic Gate Array (FPPGA)
16:25-16:40	Hyug Su Kwon <sup>1</sup> , Seok Chan Eom <sup>2</sup> , Sangyeol Oh <sup>2</sup> , Sunghoon Jang <sup>1</sup> , Changku Kim <sup>1</sup> ,
	Youngseok Bae <sup>1</sup> , Younghoon Chun <sup>2</sup> , and Sangyoon Han <sup>3</sup>
	<sup>1</sup> Agency for Defense Development, <sup>2</sup> LIG NEX <sup>1</sup> Co., Ltd., <sup>3</sup> DGIST
	Sulfur-assisted $WO_3$ Nanospheres for Enhancement of $NO_2$ Gas
FF3-I-5	Sensing
16:40-16:55	Jun-Cheol Park and Sanghan Lee
	School of Materials Science and Engineering, GIST

	Broadband Ultrahigh Responsivity Photodetector based on Topological
	Insulator/TMD Heterostructure
FF3-I-6	Hyeon seung Jo <sup>1,2</sup> , Sang il Kim <sup>3</sup> , and Tae wan Kim <sup>1,2</sup>
16:55-17:10	<sup>1</sup> Department of Electrical Engineering, Jeonbuk National University, <sup>2</sup> Smart Grid
	Research Center, Jeonbuk National University, <sup>3</sup> Department of Materials Science
	and Engineering, University of Seoul
	Modulative Artificial Nociceptor based on Double Charge Trap Layer
FF3-I-7	Structure
17:10-17:25	Geunyoung Kim and Kyung Min Kim
	Department of Materials Science and Engineering, KAIST



2024년 1월 26일(금), 15:40-17:25 Room G(201),2층

### K. Memory (Design & Process Technology) 분과

[FG3-K] NAND Flash Memory

좌장: 강대웅 교수(서울대학교), 김동찬 교수(SK Hynix University)

초청발표 FG3-K-1 15:40-16:10	Next Evolution through the Properties of 3D NAND Flash Dongchan Kim, Jinkook Kim SK hynix
FG3-K-2 16:10-16:25	HfAIO <sub>2</sub> 기반의 이중 메모리 메커니즘을 가지는 V-NAND Flash 소자의 메모 리 윈도우 및 열적 안정성 개선 추준홍, 신의중, 강창연, 김승훈, 조병진 한국과학기술원 전기 및 전자공학부
FG3-K-3 16:25-16:40	Quantitative Analysis on Z-interference Using Reprogram Scheme in 3D NAND Flash Memory V <sub>th</sub> Distribution Jooyoung Lee <sup>1</sup> and Hyungcheol Shin <sup>1,2</sup> <sup>1</sup> Seoul National University, <sup>2</sup> Integra Semiconductor Co., Ltd.
FG3-K-4 16:40-16:55	Simulation Study on the Electrical Characteristics of 3D NAND String with a Locally Deformed Memory Cell Geon-Tae Jang and Sung-Min Hong School of Electrical Engineering and Computer Science, GIST
FG3-K-5 16:55-17:10	Program Strategy of 3D NAND Flash to Mitigate Threshold Voltage Distribution Widening at Cross-Temperature Jiyoon Kim, Chanyang Park, Kihoon Nam, Donghyun Kim, Hyunseo You, and Rock- Hyun Baek Department of Electrical Engineering, POSTECH
FG3-K-6 17:10-17:25	Impacts of Hydrogen Profile on The Reliability Characteristics of Flash Memory Using SiO <sub>2</sub> /Si <sub>3</sub> N <sub>4</sub> /SiO <sub>2</sub> Stack Film by Post Annealing Sehyeon Choi <sup>1</sup> , Sejin Kim <sup>1</sup> , San Park <sup>1</sup> , Boncheol Ku <sup>1</sup> , Hanmei Choi <sup>2</sup> , Hyungjun Kim <sup>2</sup> , Jaehyun Yang <sup>2</sup> , and Changhwan Choi <sup>1</sup> <sup>1</sup> Division of Materials Science & Engineering, Hanyang University, <sup>2</sup> Memory Process Development Team, Samsung Electronics Co., Ltd.



2024년 1월 26일(금), 15:40-17:25 Room H(202),2층

### K. Memory (Design & Process Technology) 분과

[FH3-K] Ferroelectric Memory II

#### 좌장: 김상범 교수(서울대학교), 배종호 교수(국민대학교)

	High-Performance and Disturb-Free Charge Trap Flash with
FH3-K-1 15:40-15:55	Capacitance Boosting by Negative Capacitance
	Giuk Kim, Taeho Kim, Sangho Lee, Hunbeom Shin, Lingwei Zhang, Hyojun Choi,
	Yunseok Nam, Sangmok Lee, Woongjin Kim, Jihye Ock, Sujeong Lee, Hyunjun
	Kang, and Sanghun Jeon
	School of Electrical Engineering, KAIST
	Energy Efficient Computing In Memory with Metal-Ferroelectric-
	Metal-Insulator-Silicon (MFMIS) Ferroelectric FET
FH3-K-2	Giuk Kim, Sangho Lee, Hunbeom Shin, Lingwei Zhang, Hyojun Choi, Yunseok Nam,
15:55-16:10	Sangmok Lee, Woongjin Kim, Jihye Ock, Sujeong Lee, Hyunjun Kang, and Sanghun
	Jeon
	School of Electrical Engineering, KAIST
	Comparative Analysis of Polarization Switching Characteristics in
	Channel and Contact Regions of Ferroelectric InGaZnOx Thin Film
FH3-K-3	Transistor
16:10-16:25	Sejun Park, Hyojin Yang, Haesung Kim, Sanghyuk Yun, Ha Neul Lee, Dong Myong
	Kim, Dae Hwan Kim, Sung-Jin Choi, and Jong-Ho Bae
	School of Electrical Engineering, Kookmin University
	A Strategy for Controlling Imprint Field in Hafnia Ferroelectric Device
FH3-K-4	Hunbeom Shin, Junghyeon Hwang, Giuk Kim, Sangho Lee, Lingwei Zhang, Hyojun
16:25-16:40	Choi, Sujeong Lee, and Sanghun Jeon
	School of Electrical Engineering, KAIST
	Long-lifespan HfZrO4 Random-access Memory with Degradation
FH3-K-5 16:40-16:55	Suppressing Layer
	Do Yeon Lee, Woon San Ko, Jun Ho Byun, So Yeon Kwon, and Ga Won Lee
	Chungnam National University
	Termination Topologies of the Split Signal Lines for High-speed V-
FH3-K-6	NAND Package Test
16:55-17:10	Ungjin Jang, Jahwan Ku, Hyucksoo Jeon, and Sehyun Seo
	Samsung Electronics Co., Ltd.

FH3-K-7 17:00-17:25	Voltage Summation-Based Processing-In Memory SRAM Macro with
	4-Bit Weight and 4-Bit Input Using Input-Bit Slicing Method
	Jung Nam Kim <sup>1</sup> , Yong Woo Kim <sup>1</sup> , Minsuk Koo <sup>2</sup> , and Yoon Kim <sup>1</sup>
	<sup>1</sup> Department of Electrical and Computer Engineering, University of Seoul,
	<sup>2</sup> Department of Computer Science and Engineering, Incheon National University



2024년 1월 26일(금), 15:40-17:25 Room I(203),2층

D. Thin Film Process Technology 분과

[FI3-D] Emerging Films Growth Technique

좌장: 엄태용 선임(한국화학연구원), 한정환 교수(서울과학기술대학교)

초청발표	Multifunctional Oxide Thin Films for Novel Electronics
Fl3-D-1	Seung-Hyub Baek
15:40-16:10	Electronics Materials Research Center, KIST
초청발표	High-quality Thin Film Quantum Materials
FI3-D-2	Yoon Jang Chung
16:10-16:40	Department of Chemical and Biological Engineering, Korea University
FI3-D-3 16:40-16:55	Revolutionizing SnS Thin Films Fabrication for Advanced Electronics Seung Ho Ryu <sup>1,2</sup> , Minki Choe <sup>3</sup> , Taeyong Eom <sup>4</sup> , Taek-Mo Chung <sup>4</sup> , In-Hwan Baek <sup>3</sup> , and Seong Keun Kim <sup>1,2</sup> <sup>1</sup> KU-KIST Graduate School of Converging Science and Technology, Korea University, <sup>2</sup> Electronic Materials Research Center, KIST, <sup>3</sup> Department of Chemical Engineering, Inha University, <sup>4</sup> Division of Advanced Materials, KRICT



2024년 1월 26일(금), 15:40-17:25 Room J(204),2층

#### D. Thin Film Process Technology 분과

[FJ3-D] Thin Film Transistors - II

#### 좌장: 이웅규 교수(숭실대학교), 백인환 교수(인하대학교)

FJ3-D-1 15:40-15:55	Role of Post-annealing in Transistors with Oxide Channel/High-k Dielectric Stacks for 3D Stackable Memory Applications Nayeon Kim, Hyunwook Kim, Eunryeong Hong, Seonuk Jeon, and Jiyong Woo School of Electronic and Electrical Engineering, Kyungpook National University
FJ3-D-2 15:55-16:10	Impact of Channel and Blocking Layers for Fast-Speed and Low- Power Operations of Vertical Charge-Trap Memory Using InGaZnO Channel Yun-Ju Cho <sup>1</sup> , Young-Ha Kwon <sup>2</sup> , Nak-Jin Seong <sup>2</sup> , Kyu-Jeong Choi <sup>2</sup> , Hee-Ok Kim <sup>3</sup> , Jong-Heon Yang <sup>3</sup> , Chi-Sun Hwang <sup>3</sup> , and Sung-Min Yoon <sup>1</sup> <sup>1</sup> Kyung Hee University, <sup>2</sup> NCD Co., Ltd., <sup>3</sup> ETRI
FJ3-D-3 16:10-16:25	Asymmetrical Self Heating Behavior of Vertical Thin-Film Transistors with Different Source and Drain Electrode Configuration Dong-Hee Lee <sup>1</sup> , Young-Ha Kwon <sup>2</sup> , Nak-Jin Seong <sup>2</sup> , Kyu-Jeong Choi <sup>2</sup> , and Sung- Min Yoon <sup>1</sup> <sup>1</sup> Kyung Hee University, <sup>2</sup> NCD Co., Ltd.
FJ3-D-4 16:25-16:40	Effect of Source/Drain Metal-dependent Oxygen Scavenging on the Density of States and Lateral Profile of Carrier Concentration in InGaZnO TFTs Seungki Kim, Wonjung Kim, Changwook Kim, Dong Myong Kim, Sung-Jin Choi, Jong-Ho Bae, and Dae Hwan Kim School of Electrical Engineering, Kookmin University
FJ3-D-5 16:40-16:55	Comparative Analysis of Zinc-Tin-Oxide Films Grown by Atomic Layer Deposition by Varying Chemical Composition Ratio for Improved TFT Performance Dong-Hyun Lim <sup>1</sup> , Ae-Rim Choi <sup>2</sup> , Yi-Ji Jeong <sup>1</sup> , Young-Bae Ahn <sup>3</sup> , Seung-Wook Ryu <sup>3</sup> , Do-Hee Kim <sup>3</sup> , and II-Kwon Oh <sup>1,2</sup> <sup>1</sup> Department of Electrical and Computer Engineering, Ajou University, <sup>2</sup> Department of Intelligence Semiconductor Engineering, Ajou University, <sup>3</sup> Revolutionary Technology Center, R&D Division, SK hynix

	Intrinsic Device Characteristics of Oxide TFT with Morphotropic Phase
FJ3-D-6	Boundary High-к Gate Insulator by Fast ID-VG Measurement
16:55-17:10	Taeseung Jung and Sanghun Jeon
	School of Electrical Engineering, KAIST
	Improved MOSFETs Performance and Reliability by Low-temperature
FJ3-D-7	Improved MOSFETs Performance and Reliability by Low-temperature Deuterium Annealing
FJ3-D-7 17:10-17:25	

### 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

2024년 1월 26일(금), 15:40-17:25 Room K(205),2층

G. Device & Process Modeling, Simulation and Reliability 분과

[FK3-G] Device Characterization & Modeling II

좌장: 신홍식 수석(DB하이텍), 최성진 교수(국민대학교)

FK3-G-1	Effect of Oxygen Content on the Density of States and Lateral Profile of Dopant Concentration in InGaZnO FETs regarding Oxygen Scavenging
	Seong Hoon Jeon, Won Jung Kim, Changwook Kim, Jong-Ho Bae, Sung-Jin Choi,
15:40-15:55	Dong Myong Kim, and Dae Hwan Kim
	School of Electrical Engineering, Kookmin University
	Characterization of the Effects of Hydrogen and Oxygen Contents on
	Current Stress-induced Instability in the Sub-micron Amorphous
FK3-G-2	InGaZnO Thin-film Transistors based on the AC Bias Real-time Current Probe
15:55-16:10	Do Hun Kim <sup>1</sup> , Jingyu Park <sup>1</sup> , Seoung Joo Myoung <sup>1</sup> , Sangwook Kim <sup>2</sup> , Kwang-Hee
	Lee <sup>2</sup> , Jee-Eun Yang <sup>2</sup> , Younjin Jang <sup>2</sup> , and Dae Hwan Kim <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> SAIT
	Abnormal Hump Characteristic under Gated-Diode Pulse Stress and
	its Oxygen Content Effect in Sub-Micron IGZO TFTs
FK3-G-3	Su Han Noh <sup>1</sup> , Jingyu Park <sup>1</sup> , Seoung Joo Myoung <sup>1</sup> , Sangwook Kim <sup>2</sup> , Kwang-Hee
16:10-16:25	Lee <sup>2</sup> , Jee-Eun Yang <sup>2</sup> , Younjin Jang <sup>2</sup> , and Dae Hwan Kim <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> SAIT
	Annealing Process for Improving Electrical Properties of a-IGZO TFTs
	with Underlap-channel
FK3-G-4	So-Jeong Park <sup>1</sup> , Hanbin Lee <sup>1</sup> , Jeonghee Ko <sup>1</sup> , Yulim An <sup>1</sup> , Hyo-In Yang <sup>1</sup> , Gyoung-Su
16:25-16:40	Min <sup>1</sup> , Jun-Ho Jang <sup>1</sup> , Jeong-Yeon Im <sup>1</sup> , Dong Myong Kim <sup>1</sup> , Dae Hwan Kim <sup>1</sup> , Jong-
10:25-10:40	Ho Bae <sup>1</sup> , Min-Ho Kang <sup>2</sup> , and Sung-Jin Choi <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> Department of Nano-
	process, NNFC
	Highly Reliable Hump-free Multiple Channel a-InGaZnO Thin-film
	Transistor on 8-inch Wafer
FK3-G-5	Hyo-In Yang <sup>1</sup> , Hanbin Lee <sup>1</sup> , Jeonghee Ko <sup>1</sup> , Yulim An <sup>1</sup> , Gyoung-Su Min <sup>1</sup> , So-Jeong
16:40-16:55	Park <sup>1</sup> , Jun-Ho Jang <sup>1</sup> , Jeong-Yeon Im <sup>1</sup> , Dong Myong Kim <sup>1</sup> , Dae Hwan Kim <sup>1</sup> , Jong-
10.10 10.00	Ho Bae <sup>1</sup> , Min-Ho Kang <sup>2</sup> , and Sung-Jin Choi <sup>1</sup>
	<sup>1</sup> School of Electrical Engineering, Kookmin University, <sup>2</sup> Department of Nano-
	process, NNFC

FK3-G-6 16:55-17:10	Quantitative Analysis based on Subgap Density-of-States (DOS) for
	Deuterium Annealing Effect in a-IGZO TFTs by TCAD and Experimental
	Characterization
	Seongbin Lim <sup>1</sup> , Hyeonjun Song <sup>1</sup> , Jaewook Yoo <sup>1</sup> , Hongseung Lee <sup>1</sup> , Soyeon Kim <sup>1</sup> , Jo
	Hak Jeong <sup>1</sup> , Kiyoung Lee <sup>3</sup> , Hyeon-Sik Jang <sup>1</sup> , Minah Park <sup>1</sup> , Seohyeon Park <sup>1</sup> , Keun
	Heo <sup>1</sup> , Jun-Young Park <sup>2</sup> , Yoon Kyeung Lee <sup>1</sup> , and Hagyoul Bae <sup>1</sup>
	<sup>1</sup> Jeonbuk National University, <sup>2</sup> Chungbuk National University, <sup>3</sup> Hongik University
	Low-Frequency Noise and DC I-V Characterization for
	IrradiationInduced Degradation and Trap Behaviors in a-IGZO TFTs
FK3-G-7	Hongseung Lee <sup>1</sup> , Jaewook Yoo <sup>1</sup> , Hyeonjun Song <sup>1</sup> , Soyeon Kim <sup>1</sup> , Seongbin Lim <sup>1</sup> ,
17:10-17:25	Seohyeon Park <sup>1</sup> , Minah Park <sup>1</sup> , Kiyoung Lee <sup>2</sup> , Yoon Kyeung Lee <sup>1</sup> , Keun Heo <sup>1</sup> , and
	Hagyoul Bae <sup>1</sup>
	<sup>1</sup> Jeonbuk National University, <sup>2</sup> Hongik University



2024년 1월 26일(금), 15:40-17:25 Room L(206),2층

#### V. Quantum Technology 분과

#### [FL3-V] Hybrid Platform for Quantum Technology

좌장: 김도헌 교수(서울대학교)

초청발표 FL3-V-1 15:40-16:10	Hybrid Quantum Devices with Superconducting Microwave Circuits Jinwoong Cha Quantum Technology Institute, KRISS
초청발표 FL3-V-2 16:10-16:40	Quantum Acoustics: Surface Acoustic Waves-driven Single-photon Source Seok-Kyun Son <sup>1,2</sup> <sup>1</sup> Department of Physics, Kyung Hee University, <sup>2</sup> Department of Information Display, Kyung Hee University
초청발표 FL3-V-3 16:40-17:10	Graphene Straintronics for Quantum Nanodevices toward Tunable Quantum Information Nojoon Myoung Department of Physics Education, Chosun University
FL3-V-4 17:10-17:25	Tailoring of Single-electron Wave Packet along the Energy Axis Min-Sik Kim <sup>1,2</sup> , Bum-Kyu Kim <sup>2</sup> , Ju-Jin Kim <sup>1</sup> , and Myung-Ho Bae <sup>2</sup> <sup>1</sup> Department of Physics, Jeonbuk National University, <sup>2</sup> KRISS

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

### [TP1] 포스터세션 2024년 1월 25일(목) 09:00-17:55 저자 Q&A 세션: 17:15-17:55

### D. Thin Film Process Technology 분과

#### ZONE 1 (1층 전시장) Mimicking IR Visionary System via 0D-2D Heterojunction of InAs QD/WSe<sub>2</sub> Artificial Synapse TP1-001 Soobin Shim<sup>1</sup>, Hyeongtae Kim<sup>1</sup>, Seongchan Kim<sup>2</sup>, Nuri Oh<sup>2</sup>, and Jun Hong Park<sup>1</sup> <sup>1</sup>School of Materials Science & Engineering, Gyeongsang National University, <sup>2</sup>Division of Materials Science & Engineering, Hanyang University Charge Trap Engineering and Synaptic Behavior of Transition Metal Dichalcogenides Transistor, via Molecular Dynamics MiJi Kwon<sup>1</sup>, Hyeongtae Kim<sup>1</sup>, Suyeon Cho<sup>2</sup>, and Junhong Park<sup>1</sup> TP1-002 <sup>1</sup>School of Materials Science & Engineering, Gyeongsang National University, <sup>2</sup>Department of Materials Engineering and Convergence Technology, Gyeongsang National University Van Der Waals Interface Engineering for Enhancement of Semiconductor **Device Performance** Su-yeon Cho<sup>1</sup>, Do-Hyeon Lee<sup>2</sup>, and Jun Hong Park<sup>1</sup> TP1-003 <sup>1</sup>School of Materials Science & Engineering, Gyeongsang National University, <sup>2</sup>Department of Materials Engineering and Convergence Technology, Gyeongsang National University Centimeter Scaled Growth and Electric Characteristics of Layered NiTe<sub>2</sub> Wonbeom Kim<sup>1</sup>, Hyeongtae Kim<sup>2</sup>, Yeonjin Je<sup>3</sup>, Eunjeung Kim<sup>4</sup>, and Junhong Park<sup>2</sup> TP1-004 <sup>1</sup>School of Materials Science & Engineering, Gyeongsang National University, <sup>2</sup>Materials Engineering and Convergence Technology, Gyeongsang National University, <sup>3</sup>Ceramic Engineering, Gyeongsang National University, <sup>4</sup>LLNL Investigation of Annealing Effect on Indium-Zinc-Oxide (IZO) Thin Film Transistor (TFT) by Gamma-ray Radiation Do-Kywn Kim<sup>1</sup>, Dong-Seok Kim<sup>2</sup>, Min-Ju Kim<sup>1</sup>, Tae-Eon Kim<sup>1</sup>, and Seung Heon Shin<sup>3</sup> TP1-005 <sup>1</sup>Department of Semiconductor Materials and Applications, Korea Polytechnics, <sup>2</sup>Korea Multi-Purpose Accelerator Complex, KAERI, <sup>3</sup>Department of Semiconductor Process Equipment, Korea Polytechnics



TP1-006	듀얼 게이트 a-ITGZO 박막 트랜지스터의 채널 구조에 따른 전기적 특성 연구 설민혁 <sup>1</sup> , 조경아 <sup>1</sup> , 강민구 <sup>1</sup> , 김상섭 <sup>2</sup> , 김상식 <sup>1</sup> <sup>1</sup> 고려대학교 전기전자공학과, <sup>2</sup> Samsung Display Co., Ltd.
TP1-007	a-ITGZO 박막트랜지스터의 성능 향상을 위한 Al <sub>2</sub> O <sub>3</sub> /SiO <sub>2</sub> 게이트 절연막의 적용 강민구 <sup>1</sup> , 조경아 <sup>1</sup> , 김상섭 <sup>2</sup> , 김상식 <sup>1</sup> <sup>1</sup> 고려대학교 전기전자공학과, <sup>2</sup> Samsung Display Co., Ltd.
TP1-008	HfO2/InGaZnO Double-layered Transistor with Low-powered Switching Enabled by Quasi-two-dimensional Electron Channel Seyoung Oh <sup>1,2</sup> and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University, <sup>2</sup> Department of Advanced Material Engineering, Chungbuk National University
TP1-009	Influence of TiO <sub>2</sub> Thin Film Grown by Atomic Layer Deposition on N-Type Bi <sub>2</sub> Te <sub>3</sub> Se <sub>0.3</sub> Thermoelectric Powders Su Min Eun <sup>1</sup> , Ji Hyeon Hwang <sup>2</sup> , and Byung Joon Choi <sup>1</sup> <sup>1</sup> Department of Material Science and Engineering, Seoul National University of Science and Technology, <sup>2</sup> Department of Optometry, Seoul National University of Science and Technology
TP1-010	The Enhancement of the Electrical Properties of a-ZTO Thin-Film Transistors through Metal Capping Process Jin Woo Lee, Se-Hyeong Lee, So-Young Bak, Dongki Baek, Chan-Yeong Park, Hyeongrok Jang, and Moonsuk Yi Pusan National University
TP1-011	Optimization for Enhanced Electrical Properties of ZrO <sub>2</sub> /HfO <sub>2</sub> Laminated Structure for Metal-Insulator-Metal Capacitors Yoonchul Shin, Seung Won Lee, and Ji-Hoon Ahn Department of Materials Science and Chemical Engineering, Hanyang University
TP1-012	Wafer-scale Thin Film Grown WSe <sub>2</sub> via Molten Salt Method and Device Applications Sojeong Park <sup>1</sup> , Hyeongtae Kim <sup>2</sup> , Soobin Shim <sup>2</sup> , and Jun Hong Park <sup>2</sup> <sup>1</sup> Department of Energy and Mechanical Engineering, Gyeongsang National University, <sup>2</sup> School of Materials Science and Engineering, Gyeongsang National University

TP1-013	Two Step Surface Engineering of Transition Metal Dichalcogenide Heterojunction with Metal Oxide-formation and Reduction Processes Mingu Kang <sup>1</sup> and Jun Hong Park <sup>1,2</sup> <sup>1</sup> School of Materials Science and Engineering, Gyeongsang National University, <sup>2</sup> Department of Materials Engineering and Convergence Technology, Gyeongsang National University
TP1-014	Optically Simulated Synaptic Behaviors of HfS <sub>2</sub> Grown via Molten Salt Flux Method Seunghee Kim <sup>1</sup> , Mi Ji Kwon <sup>2</sup> , Jung Young Cho <sup>3</sup> , and Jun Hong Park <sup>1,2</sup> <sup>1</sup> School of Materials Science and Engineering, Gyeongsang National University, <sup>2</sup> Department of Materials Engineering and Convergence Technology, Gyeongsang National University, <sup>3</sup> Nano Convergence Materials Center, KICET
TP1-015	Low Temperature Processed, Highly Stable CMOS Inverter by integrating Zn-ON and Tellurium Thin-Film Transistors : Journal of Information Display Taeung Kim, Muhammad Naqi, Yongin Cho, and Sunkook Kim <sup>1</sup> Multifunctional Nano Bio Electronics Lab, Sungkyunkwan University, <sup>2</sup> School of Advanced Materials Science and Engineering, Sungkyunkwan University
TP1-016	Intense Pulsed Light을 이용한 선택적 어닐링을 통한 Top-gate Self-aligned 구조의 IGZO TFT 성능 개선 김희태 <sup>1</sup> , 박서학 <sup>1</sup> , 정재중 <sup>1</sup> , 박영근 <sup>1</sup> , 김동빈 <sup>1</sup> , 조성행 <sup>2</sup> , 최성율 <sup>1</sup> , 조병진 <sup>1</sup> <sup>1</sup> 한국과학기술원 전기 및 전자공학부, <sup>2</sup> 한국전자통신연구원 플렉시블전자소자연구실
TP1-017	Unlocking the Functionality of Multi-phase Tungsten Disulfide for Negative Differential Resistance and Random-access Memory Devices Jinill Cho <sup>1</sup> , Gunhoo Woo <sup>2</sup> , Jinhyeong Lee <sup>1</sup> , and Taesung Kim <sup>1,2</sup> <sup>1</sup> School of Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> SKKU Advanaced Institute of Nanotechnology, Sungkyunkwan University
TP1-018	Multi-stack Ferroelectric Capacitor based on Fluorite Structure Materials for Neuromorphic Computing Hyo-Bae Kim and Ji-Hoon Ahn Department of Materials Science and Chemical Engineering, Hanyang University
TP1-019	Multilevel Block Copolymers and Polymer Colloids Composites for Sensitive Gas Sensor Dong Won You, Geon Gug Yang, and Sang Ouk Kim Department of Material Science & Engineering, KAIST

TP1-020	Tungsten Diselenide (WSe <sub>2</sub> ) Ambipolar Transistor with Al <sub>2</sub> O <sub>3</sub> Passivation Supported by Ultrathin Al layer for High-stability Logic device Joo-On OH and Sunkook Kim School of Advanced Materials Science & Engineering, Sungkyunkwan University
TP1-021	Composition-controllable Growth of GeTe Thin Films by Hollow Cathode Plasma-assisted Atomic Layer Deposition Min Gyoo Cho, Ju Hwan Park, Si Eun Jung, and Byung Joon Choi Department of Material Science and Engineering, Seoul National University of Science and Technology
TP1-022	High-performance of Hydrogenated Spinel Phase InZnSnO Thin-Film Transistors Gwang-Bok Kim and Jae Kyeong Jeong Department of Electronic Engineering, Hanyang University
TP1-023	Hydrogen Behavior in Oxide TFTs with Gate Insulator Variation by High- pressure Hydrogen Annealing Jin Won Bak and Jae Kyeong Jeong Department of Electronic Engineering, Hanyang University
TP1-024	Hydrogen Doped a-IGZTO TFTs with Excellent Reliability and High Field- effect Mobility Sang Won Chung and Jae Kyeong Jeong Department of Electronic Engineering, Hanyang University
TP1-025	Effect of Ti Interlayer on Ferroelectric HZO Thin Film Jaeyoung Joo, Ju-young Jeong, Yoogeun Han, and Hyunchul Sohn Department of Materials Science and Engineering, Yonsei University
TP1-026	Optimization of AI-doped HfO <sub>2</sub> /ZrO <sub>2</sub> Layered Structure for Improving Electrical Characteristics Yeon-Ji Jeon, Seung Won Lee, and Ji-Hoon Ahn Department of Materials Science and Chemical Engineering, Hanyang University
TP1-027	Investigation of IWO TFT for Enhanced Electrical Performance and Long- term Stability Compared to IGZO TFT Hyun-Sik Choi, Ki-Ju Park, and Won-Ju Cho Department of Electronic Materials Engineering, Kwangwoon University

TP1-028	Inherent Area-selective Atomic Layer Deposition of SiO <sub>2</sub> Quang Khanh Nguyen, Juyeong Lee, and Myung Mo Sung Department of Chemistry, Hanyang University
TP1-029	Inducing the Tetragonal-phase HfO <sub>2</sub> in ZrO <sub>2</sub> /HfO <sub>2</sub> Stack by Introducing the Controlled Interfacial Layer Woo Young Park <sup>1,2</sup> , In kyu Lee <sup>1,2</sup> , Young Uk Ryu <sup>1,2</sup> , and Woojin Jeon <sup>1,2</sup> <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University
TP1-030	Hybrid Reactant of HfO <sub>2</sub> Atomic Layer Deposition Process for Metal- insulator-metal Capacitor Applications In Gyu Lee <sup>1,2</sup> , Woo Young Park <sup>1,2</sup> , Young Uk Ryu <sup>1,2</sup> , and Woojin Jeon <sup>1,2</sup> <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University
TP1-032	Effects of Electrode Configuration on the Electrical Properties of PEALD HZO Ferroelectric capacitors Ha Jeong Kim, Won Ji Park, and Hee Chul Lee Department of Advanced Materials Engineering, Tech University of Korea
TP1-033	Characterization of HZO Films Prepared by Co-Plasma Atomic Layer Deposition for Ferroelectric Memory Application Won Ji Park, Jae Hoon Yu, and Hee Chul Lee Department of Advanced Materials Engineering, Tech University of Korea
TP1-034	Study of Reactant Gas Characteristics of Silicon Nitride Thin Film Deposited Using 27.12 MHz Frequency B.J. Lee <sup>1,2</sup> , H.C. Cho <sup>1,2</sup> , M.H. Cheon <sup>1,2</sup> , H.S. Ru <sup>1,2</sup> , H.C. Moon <sup>1,2</sup> , R. Woo <sup>1,2</sup> , D.W. Seo <sup>1,2</sup> , and J.W. Choi <sup>1,2</sup> <sup>1</sup> Vacuum Equipment R&D Division, Hanwha Corporation, <sup>2</sup> Semiconductor Research Center, Hanwha Corporation
TP1-035	Failure Analysis of Ovonic Threshold Switch from a Thermal Perspective Ju Hwan Park <sup>1</sup> , Myeong Jun Jung <sup>1</sup> , Hyun Wook Kim <sup>1</sup> , Su Yeon Lee <sup>2</sup> , Jae Hyuck Jang <sup>3</sup> , Gun Hwan Kim <sup>4</sup> , Min Kyu Yang <sup>2</sup> , and Byung Joon Choi <sup>1</sup> <sup>1</sup> Dept. of Materials Science and Engineering, Seoul National University of Science and Technology, <sup>2</sup> Division of Al Convergence Engineering, Sahmyook University, <sup>3</sup> Electron Microscopy and Spectroscopy Team, KBSI, <sup>4</sup> Dept. of Materials Science and Engineering,



TP1-036	SuperiorInfraredReflectanceandSheetResistanceofITO/Ag/ITO/Ag/ITO(IAIAI)StructureasElectrodeofTransparentPhotovoltaicsChanhyuk Choi, JungHyun Lee, and Joondong KimDepartment of Electrical Engineering, Incheon National University
TP1-037	Functional Design of Optically Transparent Windows by Using Macleod Simulation JungHyun Lee, ChanHyuk Choi, and Joondong Kim Incheon National University
TP1-038	Implementation of Integrate-and-Fire (IF) Characteristics Using Oxide- based 1T-Neuron Jaehee Lee <sup>1,2</sup> , Jieun Kim <sup>1,2</sup> , and Jung Wook Lim <sup>1,2</sup> <sup>1</sup> ETRI, <sup>2</sup> UST
TP1-039	Development of Visible-NIR Responsive Nanoporous Morphology on Large-scale IGZO and Realization of High-performance Image Sensor Jaeseong Kim, Anamika Sen, Chaeyoung Im, and Sunkook Kim Department of Advanced Materials Science Engineering, Sungkyunkwan University
TP1-040	TiO <sub>2</sub> Interlayer를 이용한 AI/ZnO 접촉저항 개선 윤성빈 <sup>1,2</sup> , 김기영 <sup>1,2</sup> , 이해원 <sup>1,2</sup> , 김민재 <sup>1,2</sup> , 황현준 <sup>1,2</sup> , 이병훈 <sup>1,2</sup> <sup>1</sup> CSTC, POSTECH, <sup>2</sup> Department of Electrical Engineering, POSTECH
TP1-041	Enhanced Performance and Stability of 2D Sn Halide Perovskite Transistor by Incorporating Alkylammonium Halide Additives Hakjun Kim, Bum Ho Jeong, Jongmin Lee, and Hui Joon Park Department of Organic and Nano Engineering, Hanyang University
TP1-042	극박막 상복합 ZnO 영미분전도소자의 1/f 노이즈 특성 연구 이해원 <sup>1,2</sup> , 김승모 <sup>1,2</sup> , 이용수 <sup>1,2</sup> , 김민재 <sup>1,2</sup> , 전재현 <sup>1,2</sup> , 황현준 <sup>1,2</sup> , 이병훈 <sup>1,2</sup> <sup>1</sup> CSTC, POSTECH, <sup>2</sup> Department of Electrical Engineering, POSTECH
TP1-043	Performance Improvement of Indium Oxide TFTs with Tungsten Doping Juwon Kim <sup>1</sup> , Hyun-Sik Choi <sup>2</sup> , Won-Ju Cho <sup>2</sup> , and Hamin Park <sup>1</sup> <sup>1</sup> Department of Electronic Engineering, Kwangwoon University, <sup>2</sup> Department of Electronic Materials Engineering, Kwangwoon University



TP1-044	플라즈마 처리를 이용한 Tellurium FET 의 히스테리시스 개선 김규헌 <sup>1,2</sup> , 김민재 <sup>1,2</sup> , 이용수 <sup>1,2</sup> , 김승모 <sup>1,2</sup> , 이해원 <sup>1,2</sup> , 황현준 <sup>1,2</sup> , 이병훈 <sup>1,2</sup> <sup>1</sup> CSTC, POSTECH, <sup>2</sup> Department of Electrical Engineering, POSTECH
TP1-045	수직 적층 공정을 이용한 ZnO/Te 상보형 전계 효과 트랜지스터 김기영 <sup>1,2</sup> , 김민재 <sup>1,2</sup> , 이용수 <sup>1,2</sup> , 이해원 <sup>1,2</sup> , 전재현 <sup>1,2</sup> , 윤성빈 <sup>1,2</sup> , 황현준 <sup>1,2</sup> , 이병훈 <sup>1,2</sup> <sup>1</sup> CSTC, POSTECH, <sup>2</sup> Department of Electrical Engineering, POSTECH
TP1-046	Stable Ferroelectric Properties of Sub-5 nm Hafnium-Zirconium-Oxide Thin Films Deposited via Atomic Layer Deposition Gunho Kim <sup>1</sup> , Hyo-Bae Kim <sup>1</sup> , Wonwoo Kho <sup>2</sup> , Yoomi Kang <sup>2</sup> , Seung-Eon Ahn <sup>3</sup> , and Ji- Hoon Ahn <sup>1</sup> <sup>1</sup> Department of Materials Science and Chemical Engineering, Hanyang University, <sup>2</sup> Department of IT · Semiconductor Convergence Engineering, Tech University of Korea, <sup>3</sup> Department of Nano & Semiconductor Engineering, Tech University of Korea
TP1-047	Fabrication of TiO <sub>2</sub> Dispersion Strengthened Nb-based Alloy by Atomic Layer Deposition Ji Young Park, Ji Hyeon Jeon, Sumin Eun, Eui Seon Lee, Eunho Ma, Min Seob Jeong, Byoungchul Hwang, Jongmin Byun, Sung-Tag Oh, and Byung Joon Choi Department of Materials Science and Engineering, Seoul National University of Science and Technology
TP1-048	Thermal ALD Novel Mo Precursor for Low Resistivity MoN Thin Film Formation Myeong-Ho Kim, Yun-Gyeong Yi, Su-min Kim, In-Jae Lee, and Jin-Sik Kim UP Chemical
TP1-049	Physical Properties of GeS <sub>x</sub> Thin Films Deposited by RF Sputtering Ju Sung Kim, Wan Sun Kim, and Hyunchul Sohn Department of Materials Science and Engineering, Yonsei University
TP1-050	Threshold Switching Characteristics of (ZnTe) <sub>x</sub> (ZnS) <sub>1-x</sub> Chalcogenide Alloy Deposited by RF Sputtering Wansun Kim, Jusung Kim, and Hyunchul Sohn Department of Materials Science and Engineering, Yonsei University

TP1-051	Achieving Molecular Alignment in Semiconducting Polymers: A Step towards Improved Electrical Performance Jin Seok Yoon, Nak Hee Kang, Sam Nyung Yi, Hyung Soo Ahn, Kyung Hwa Kim, and Young Tea Chun Division of Electronics and Electrical Information Engineering, Korea Maritime and Ocean University Atomic Layered Deposition of SnO <sub>2</sub> Thin Films Using a Novel Sn
TP1-052	Precursor Jeong Eun Shin <sup>1</sup> , Heesun Kim <sup>2</sup> , Bo Keun Park <sup>2</sup> , and Jeong Hwan Han <sup>1</sup> <sup>1</sup> Department of Materials Science and Engineering, Seoul National University of Science and Technology, <sup>2</sup> Thin Film Materials Research Center, KRICT
TP1-053	Effect of Electrodes on (NiO) <sub>x</sub> (La <sub>2</sub> O <sub>3</sub> ) <sub>1-x</sub> Thin Films Jeongwoo Lee and Hyunchul Sohn Department of Materials Science and Engineering, Yonsei University
TP1-054	40.68 & 60 MHz 주파수를 이용한 2단계 PE-ALD 공정이 적용된 Silicon Nitride 박막의 특성 비교 Da-Eun Bae <sup>1</sup> , Hyung Min Kim <sup>1</sup> , Sang Ick Lee <sup>2</sup> , Jae Ho Choi <sup>1</sup> , and Jae Hak Jeong <sup>1</sup> <sup>1</sup> CN <sup>1</sup> Co., Ltd., <sup>2</sup> DNF Co., Ltd.
TP1-055	Random-Network Silicon Nanowire Channel Based High-Performance Ca <sup>2+</sup> -Selective Dual-Gate Ion Sensitive Field-Effect Transistors Tae-Gyu Hwang, Tae-Hwan Hyun, and Won-Ju Cho Department of Electronic Materials Engineering, Kwangwoon University
TP1-056	Morphotropic Phase Boundary 구조를 갖는 Hf 유전막 특성 연구 이찬빈, 김승모, 황현준, 이병훈 CSTC, Department of Electrical Engineering, POSTECH
TP1-057	Thermal Annealing of Solution-Processed P-type NiO Transistor Yerim Lee <sup>1</sup> , Tae-Gyu Hwang <sup>2</sup> , Won-Ju Cho <sup>2</sup> , and Hamin Park <sup>1</sup> <sup>1</sup> Department of Electronic Engineering, Kwangwoon University, <sup>2</sup> Department of Electronic Materials Engineering, Kwangwoon University
TP1-058	Supercycle of AlO and HfO Using Atomic Layer Deposition for Nanolaminate Capacitor Hyunseok Son, Beomhee Yoon, Hyunho Lee, and Hamin Park Department of Electronic Engineering, Kwangwoon University

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TP1-059	LiNbO <sub>3</sub> Thin Film for Photonics Devices by Sputtering Method Namhoon Kim <sup>1,2</sup> , Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> KIST, <sup>2</sup> Department of Material Science and Engineering, Yonsei University, <sup>3</sup> School of Electrical Engineering, Korea University
TP1-060	Study of Metal-doped Zinc Oxide-Based Electron Extraction Layer to Improved Performance of Inverted Organic Photodetectors Jaebum Jeong and Jun Young Kim Department of Semiconductor Engineering, Gyeongsang National University
TP1-061	A Study of Defect Control Through Heat Transfer in a Furnace System Daeman Seo <sup>1,2</sup> , Sungman Lee <sup>1</sup> , Sungho Jegal <sup>1</sup> , Seungjae Baek <sup>1</sup> , and Inho Lee <sup>2</sup> <sup>1</sup> Device Solution, Samsung Electronics Co., Ltd., <sup>2</sup> Major of Electronic Engineering, Hankyong National University
TP1-062	Analysis of Growth Behavior and Electrical Property of TiO <sub>2</sub> Thin Film by Atomic Layer Deposition Jae Hun Hwang, Jong ho Song, and Taeyong Eom Thin Film Materials Research Center, KRICT
TP1-063	Demonstration of Atomic Layer Deposition of BeO Using Discrete Feeding Method JongHyun Bae <sup>1</sup> , YoonSeo Jang <sup>1</sup> , Juyung Chae <sup>1</sup> , Christopher W. Bielawski <sup>2</sup> , and Jungwoo Oh <sup>1</sup> <sup>1</sup> School of Integrated Technology, Yonsei University, <sup>2</sup> CMCM IBS, Department of Chemistry, UNIST
D Thin Film Process Technology 부과	

#### ZONE 2 (2층 로비)

TP1-064	Understanding Al <sub>2</sub> O <sub>3</sub> Infiltration in PDMS via Atomic Layer Deposition Pengfei Liu <sup>1</sup> and In Soo Kim <sup>1,2</sup> <sup>1</sup> KIST, <sup>2</sup> Sungkyunkwan University

	Accurate Regulation of Dopant Distribution in both Lateral and Vertical
	Directions in Sn-doped $In_2O_3$ Grown via Atomic Layer Deposition
TP1-065	Tae Seok Kim <sup>1,2</sup> , Han Kim <sup>1,2</sup> , and Seong Keun Kim <sup>1,2</sup>
	<sup>1</sup> KU-KIST Graduate School of Converging Science and Technology, Korea University,
	<sup>2</sup> Electronic Materials Research Center, Korea Institute of Science and Technology
	Growth Characteristics and Film Properties of Molybdenum Oxide Thin
	Films by Atomic Layer Deposition with Different Oxygen Sources
TP1-066	Haram Yang <sup>1</sup> , Hyeongjun Kim <sup>2</sup> , and Woongkyu Lee <sup>1</sup>
	<sup>1</sup> Department of Materials Science and Engineering, Soongsil University, <sup>2</sup> Department
	of Green Chemistry and Materials Engineering, Soongsil University
	Novel Molybdenum N-alkoxy Carbothioamide Complexes for 2D $MoS_2$
	Thin Films
TP1-067	Sung Kwang Lee <sup>1,2</sup> , Seung Uk Son <sup>2</sup> , and Taek-Mo Chung <sup>1,3</sup>
11 1 007	<sup>1</sup> Thin Film Materials Research Center, Korea Research Institute of Chemical
	Technology, <sup>2</sup> Department of Chemistry, Sungkyunkwan University, <sup>3</sup> Department of
	Chemical Convergence Materials, UST
	Inhibitor Assisted Si-HfO <sub>2</sub> ALD Process to Improve Si Doping Uniformity
TD1 000	Duck Hyeon Seo, Jae Min Kim, Ha Na Kim, Ji Yeon Han, Hyeon Sik Cho, Ju Hwan
TP1-068	Jung, Hyun Ju Jung, Sun Young Baik, and Kyu Ho Cho
	EGTM Co. R&D Center
	Characterization of Capacitors with ITO/HfAIO(HAO)/ITO Structures
	Deposited by RF-sputtering Operted at Low Frequency
TP1-069	In-Pyo Hong, He Rui, Ma-Ro Kim, and Chung Wung Barki
	Gachon University
	Improving Electrical Properties Using New Al Precursor for Doping
TP1-070	Sung-Woo Ahn, Jae-Young Min, Ki-Chang Song, and Dr. Jin-Sik Kim
11 1 070	UP Chemical
	Characteristics of Molybdenum Dioxide Atomic Layer Deposition
TP1-071	Process
	Hyun-June Park, Min-Su Cho and Sung-Woong Chung
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	Experimental Realization Strain-induced Room Temperature
	Ferroelectricity in SrMnO $_3$ Thin Films on Si and Nb-SrTiO $_3$ Substrates
TP1-072	through RF-sputtering High-Temperature Depositation
	Rui He, Maro Kim, and ChungWung Bark
	Gachon University

TP1-073	Delay Time Variation with Applied Voltage Pulses in Te-Based Ovonic Threshold Switching Selectors Sangyeop Kim <sup>1,2</sup> , Young-Min Kim <sup>1,2</sup> , Su-Bong Lee <sup>1</sup> , and Jong–Souk Yeo <sup>1,2</sup> <sup>1</sup> School of Integrated Technology, College of Computing, Yonsei University, <sup>2</sup> BK21 Graduate Program in Intelligent Semiconductor Technology
TP1-074	Growth of Scandium – doped Aluminum Nitride Thin Films by Plasma Enhanced Atomic Layer Deposition Seung Hoon Oh, Hyoeun Roh, and Taeyong Eom Thin Film Materials Research Center, Korea Research Institute of Chemical Technology
TP1-075	Ferroelectricity of HfxZr <sub>1-x</sub> O <sub>2</sub> Thin Films Deposited on Epitaxial TiN Bottom Electrodes Yoogeun Han, Ju-Young Jeong, Jaeyoung Joo, and Hyunchul Sohn Department of Materials Science and Engineering, Yonsei University
TP1-076	New Tin Sulfide Precursor for Semiconductor Materials Heenang Choi <sup>1,2</sup> and Taek-Mo Chung <sup>1,3</sup> <sup>1</sup> Thin Film Materials Research Center, KRICT, <sup>2</sup> Department of Chemistry, SKKU, <sup>3</sup> Department of Chemical Convergence Materials, UST
TP1-077	Atomic Layer Deposition of In <sub>2</sub> O <sub>3</sub> with Different Temperatures for n-Type Oxide Semiconductors Kyunghun Lyu <sup>1</sup> , Jaejun Lee <sup>2</sup> , and Woongkyu Lee <sup>1,2</sup> <sup>1</sup> Department of Materials Science and Engineering, Soongsil University, <sup>2</sup> Department of Green Chemistry and Materials Engineering, Soongsil University
TP1-078	Combined Experimental and DFT Analysis of Initial Adsorption Behavior in ZfHfO <sub>2</sub> Thin Films on TiN Surface Jeong Hyeon Park, Jenam Kim, and Woojin Jeon Department of Advanced Materials Engineering for Information and Electronics, and Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University

TP1-079	Enhancement of Resistance Switching Behavior of Au/TiO <sub>2</sub> /Au Memristors on PDMS Substrate with Pyramid Structure Jaejun Lee <sup>1</sup> , Kyunghun Lyu <sup>2</sup> , and Woongkyu Lee <sup>1,2</sup> <sup>1</sup> Department of Green Chemistry and Materials Engineering, Soongsil University, <sup>2</sup> Department of Materials Science and Engineering, Soongsil University
TP1-080	Effects on Electrical Properties of TiO <sub>2</sub> -Based Capacitors by Improving Bulk and Interface Properties Taehyun Kim <sup>1</sup> , Daeun Lim <sup>2</sup> , Juan Hong <sup>2</sup> , and Woongkyu Lee <sup>1,2</sup> <sup>1</sup> Department of Green Chemistry and Materials Engineering, Soongsil University, <sup>2</sup> Department of Materials Science and Engineering, Soongsil University
TP1-081	Contact Resistance Improvement of a-IGZO TFT by Inserting ALD Based AZO Interlayer Dongseon Kim and Jae Kyeong Jeong Department of Electronic Engineering, Hanyang University
TP1-082	Development of High-performance Broadband Photodetectors Using Hydrogen Plasma-treated IGZO Thin Films Hyun yeol Rho <sup>1</sup> , Arindam Bala <sup>2</sup> , and SunKook Kim <sup>1</sup> <sup>1</sup> Multifunctional Nano Bio Electronics Lab, School of Advanced Materials Science and Engineering, Sungkyunkwan University, <sup>2</sup> Swiss Federal Institute of Technology Lausanne
TP1-083	Growth of Highly Dense and Conformal GeSe Thin Films by Thermal Atomic Layer Deposition Ye Bin Weon <sup>1</sup> , Hyunwook Kim <sup>1</sup> , Junyoung Lim <sup>2</sup> , David Ahn <sup>2</sup> , and Byung Joon Choi <sup>1</sup> <sup>1</sup> Department of Materials Science and Engineering, Seoul National University of Science and Technology, <sup>2</sup> R&D Division, SK hynix Inc.
TP1-084	Study on Multi-layer Stacking Effects of Oxide-Based Thin-films Jinyeong Lee, Sungbin Jo, and Jaewook Jeong School of Information and Communication Engineering, Chungbuk National University
TP1-085	Atomic Layer Deposition of Ir Thin Films with Tricarbonyl (1,2,3,-η)- 1,2,3-tri(tert-butyl)-cyclopropenyl Iridium (TICP) and O <sub>3</sub> Han Kim <sup>1,2</sup> , Hong Keun Chung <sup>2,3</sup> , Tae Seok Kim <sup>1,2</sup> , and Seong Keun Kim <sup>1,2</sup> <sup>1</sup> KU-KIST Graduate School of Converging Science and Technology, Korea University, <sup>2</sup> Electronic Materials Research Center, KIST, <sup>3</sup> Department of Materials Science and Chemical Engineering, Hanyang University

TP1-086       Enhancing the Electrical Properties of TiN/Zr0 <sub>2</sub> /TiN MIM Capacitor with In <sub>2</sub> O <sub>3</sub> Buffer Layer by Atomic Layer Deposition Vona Choi <sup>1,2</sup> , Seungwoo Lee <sup>1,2</sup> , Donghyun Kim <sup>3</sup> , Hansol Oh <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin Jeon <sup>1,2</sup> TP1-086       "Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>3</sup> Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-087       Controlling Electrical Properties of Zr0 <sub>2</sub> -Based Metal-insulator-metal Capacitor via Gd Doping without Sacrificing Tetragonality Seungwoo Lee <sup>1,2</sup> , Yoona Choi <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Dh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> TP1-087       Controlling Electrical Properties of Zr0 <sub>2</sub> -Based Metal-insulator-metal Capacitor via Gd Doping without Sacrificing Tetragonality Seungwoo Lee <sup>1,2</sup> , Yoona Choi <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Dh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> TP1-087       Thermal Atomic Layer Deposition of Information and Electronics, Kyung Hee University, <sup>3</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>2</sup> ) Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi		
TP1-086       Yoona Choi <sup>1,2</sup> , Seungwoo Lee <sup>1,2</sup> , Donghyun Kim <sup>3</sup> , Hansol Oh <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin Jeon <sup>1,2</sup> <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         Controlling Electrical Properties of ZrO <sub>2</sub> -Based Metal-insulator-metal Capacitor via Gd Doping without Sacrificing Tetragonality Seungwoo Lee <sup>1,2</sup> , Yoona Choi <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> TP1-087 <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         Tris(dimethylamido)gallium and Ammonia       Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong University         Thermal Atomic Layer Deposition of Gallium Nitride Films using Tris(dimethylamido)gallium and Ammonia       Study of Electrical Propert		Enhancing the Electrical Properties of TiN/ZrO <sub>2</sub> /TiN MIM Capacitor with
<sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-087       Controlling Electrical Properties of ZrO <sub>2</sub> -Based Metal-insulator-metal Capacitor via Gd Doping without Sacrificing Tetragonality Seungwoo Lee <sup>1,2</sup> , Yoona Choi <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Chol <sup>2</sup> , and Donghee Park <sup>1</sup>		$In_2O_3$ Buffer Layer by Atomic Layer Deposition
<sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-087       Controlling Electrical Properties of ZrO <sub>2</sub> -Based Metal-insulator-metal Capacitor via Gd Doping without Sacrificing Tetragonality Seungwoo Lee <sup>1,2</sup> , Yoona Choi <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Chol <sup>2</sup> , and Donghee Park <sup>1</sup>		Yoona Choi <sup>1,2</sup> , Seungwoo Lee <sup>1,2</sup> , Donghyun Kim <sup>3</sup> , Hansol Oh <sup>3</sup> , Yongjoo Park <sup>3</sup> , and
Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-087       Controlling Electrical Properties of ZrO <sub>2</sub> -Based Metal-insulator-metal Capacitor via Gd Doping without Sacrificing Tetragonality Seungwoo Lee <sup>1,2</sup> , Yoona Cho <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> TP1-087       Seungwoo Lee <sup>1,2</sup> , Yoona Cho <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> Tuppartment of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering         Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Chol <sup>2</sup> , and Donghee Park <sup>1</sup> 'Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of	TP1-086	Woojin Jeon <sup>1,2</sup>
Technology (BK21 Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         Controlling Electrical Properties of Zr02-Based Metal-insulator-metal Capacitor via Gd Doping without Sacrificing Tetragonality Seungwoo Lee <sup>1,2</sup> , Yoona Cho <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> 'Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>3</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee         Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering         Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> 'Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		
Team, SK Trichem Co., Ltd.         Controlling Electrical Properties of ZrO2-Based Metal-insulator-metal Capacitor via Gd Doping without Sacrificing Tetragonality Seungwoo Lee <sup>1,2</sup> , Yoona Choi <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongioo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> TP1-087       Pbepartment of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>3</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> TP1-090       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> TP1-090       Fuer for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KI		
TP1-087Capacitor via Gd Doping without Sacrificing Tetragonality Seungwoo Lee <sup>1,2</sup> , Yoona Chol <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.TP1-088Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong UniversityTP1-089Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong UniversityTP1-089Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		
TP1-087       Seungwoo Lee <sup>1,2</sup> , Yoona Choi <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> , Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> . <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee         Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089         TP1-090         TP1-090         Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Sem		Controlling Electrical Properties of ZrO <sub>2</sub> -Based Metal-insulator-metal
TP1-087       Hanbyul Kim <sup>3</sup> , Yongjoo Park <sup>3</sup> , and Woojin jeon <sup>1,2</sup> <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Tricherm Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> 'Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		Capacitor via Gd Doping without Sacrificing Tetragonality
<sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         0khyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> TP1-090       Study of Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		Seungwoo Lee <sup>1,2</sup> , Yoona Choi <sup>1,2</sup> , Jonghwan Jeong <sup>1,2</sup> , Jihun Nam <sup>1,2</sup> , Han sol Oh <sup>3</sup> ,
Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science & Technology (BK <sup>21</sup> Four), Kyung Hee University, <sup>3</sup> Advanced Research Development Team, SK Trichem Co., Ltd.         TP1-088       Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering         Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of	IP1-087	
Team, SK Trichem Co., Ltd.         Thermal Atomic Layer Deposition of Aluminum Nitride Thin Film Using Tris(dimethylamido)aluminum and Ammonia         Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee         Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089         Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee         Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089         TP1-080         Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		Kyung Hee University, <sup>2</sup> Integrated Education Program for Frontier Science &
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TP1-088Tris(dimethylamido)aluminum and Ammonia Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong UniversityTP1-089Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong UniversityTP1-089Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		
TP1-088       Okhyeon Kim, Hyunmin Han, Yerim Choi, Jian Heo, Changgyu Kim, Hye-Lee Kim, and Won-Jun Lee         Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering         Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		
IPI-088       Won-Jun Lee         Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering         Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		
Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong University         TP1-089       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> TP1-090       Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of	TP1-088	
University         TP1-089         Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		
TP1-089       Thermal Atomic Layer Deposition of Gallium Nitride Films Using Tris(dimethylamido)gallium and Ammonia         Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering       Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		
TP1-089Tris(dimethylamido)gallium and Ammonia Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong UniversityTP1-080Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		
TP1-089Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee Department of Nanotechnology and Advanced Materials Engineering, Sejong UniversityStudy of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		Thermal Atomic Layer Deposition of Gallium Nitride Films Using
TP1-090       Department of Nanotechnology and Advanced Materials Engineering, Sejong University         Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering         Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		Tris(dimethylamido)gallium and Ammonia
University         Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of	TP1-089	Yerim Choi, Okhyeon Kim, Jian Heo, Hye-Lee Kim, and Won-Jun Lee
TP1-090       Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by Reactive Sputtering         Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		Department of Nanotechnology and Advanced Materials Engineering, Sejong
TP1-090 Reactive Sputtering Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		University
TP1-090 Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		Study of Electrical Properties of Vanadium Dioxide Thin Films on TiN by
TP1-090       Donghee Park <sup>1</sup> <sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor         Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of	TP1-090	Reactive Sputtering
<sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		Seunghwi Koo <sup>1,2</sup> , Haeri Park <sup>1,3</sup> , Namhoon Kim <sup>1,2</sup> , Roju Chae <sup>1,3</sup> , Heonjin Choi <sup>2</sup> , and
Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		Donghee Park <sup>1</sup>
Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of		<sup>1</sup> Center for Opto-Electronic Materials and Devices, Post-Silicon Semiconductor
Electrical Engineering, Korea University		Institute, KIST, <sup>2</sup> Materials Science and Engineering, Yonsei University, <sup>3</sup> School of
		Electrical Engineering, Korea University

	Preparation of Cubic-phase-stabilized Y-doped ZrO <sub>2</sub> Nanoparticles and
	Thin Films by Solution Methods for SOFC Application
TP1-091	Taeyoon Kim <sup>1</sup> , Yunbin Kim <sup>2</sup> , and Sangmoon Park <sup>1,2,3</sup>
181-091	<sup>1</sup> Department of Electronics-Energy Materials, Silla University, <sup>2</sup> Division of Energy and
	Chemical Engineering Major in Energy and Applied Chemistry, Silla University,
	<sup>3</sup> Department of Fire Protection and Safety Management, Silla University
	Strategies for Precision Control of the Interfacial Layer in ZrO2(or
	HfO <sub>2</sub> )/TiN Structures for DRAM Capacitors
TP1-092	Myoung Su Jang <sup>1,2</sup> , Ji Hoon Jeon <sup>1,2</sup> , Taikyu Kim <sup>2</sup> , and Seong Keun Kim <sup>1,2</sup>
	<sup>1</sup> KU-KIST Graduate School of Converging Science and Technology, Korea University,
	<sup>2</sup> Electronic Materials Research Center, KIST
	Variation in Carrier Concentration and Sheet Resistance of Atomic-Layer
	Deposited InGaSnO Thin Films with Controlling Process Temperatures
TP1-093	Jae-Hyuk Yoo <sup>1</sup> , Shin-Ho Noh <sup>1</sup> , Young-Ha Kwon <sup>2</sup> , Nak-Jin Seong <sup>2</sup> , Kyu-Jeong Choi <sup>2</sup> ,
	and Sung-Min Yoon <sup>1</sup>
	<sup>1</sup> Kyung Hee University, <sup>2</sup> NCD Co., Ltd.
	Effects of Crystal Structures of $TiO_{2-x}$ Film on Their Thermistor
	Resistance
TP1-094	Haeri Park <sup>1,2</sup> , Jeongeun Mo <sup>1,3</sup> , Won jun Choi <sup>1</sup> , Gyutae Kim <sup>2</sup> , and Donghee Park <sup>1</sup>
	<sup>1</sup> KIST, <sup>2</sup> School of Electrical Engineering, Korea University, <sup>3</sup> School of Advanced
	Materials Science and Engineering, Sungkyunkwan University
	Dielectric Engineering for High-Performance Top Gate SnO Thin-Film
	Transistors toward Vertically Stacked Complementary Inverters
	MinKi Choe <sup>1</sup> , Seung Ho Ryu <sup>2,3</sup> , Taeyong Eom <sup>4</sup> , Taek-Mo Chung <sup>4</sup> , Seong Keun Kim <sup>2,3</sup> ,
TP1-095	and In-Hwan Baek <sup>1</sup>
	<sup>1</sup> Department of Chemical Engineering, Inha University, <sup>2</sup> KU-KIST Graduate School of
	Converging Science and Technology, Korea University, <sup>3</sup> Electronic Materials Research
	Center, KIST, <sup>4</sup> Division of Advanced Materials, KRICT
TP1-096	Area-selective-deposition (ASD) of Ruthenium (Ru) Thin Film Using Self-
	assembled Monolayer (SAM) through Surface Modification
	Ji hyeon Sim, Chae Won Kim, Hyun Jin Lim, Ki Sub Kim, Hyeong Jun Kim, Hyo Jin
	Ahn, and Changhwan Choi
	Division of Materials Science and Engineering, Hanyang University

TP1-097	Tailoring of Ferroelectric Coercive Field and Polarization of MFM Capacitors with Hf <sub>x</sub> Zr <sub>1-x</sub> O <sub>2</sub> Bilayer Structure Geon Park and Rino Choi 3D Convergence Center and Materials Science and Engineering, Inha University
TP1-098	Optoelectronic-synaptic Properties of ReS <sub>2</sub> /MoS <sub>2</sub> Hetero-structure Synthesized by Chemical Vapor Deposition Dong Geun Kim, Seung Won Lee, and Ji-Hoon Ahn Department of Materials Science and Chemical Engineering, Hanyang University
TP1-099	Correlation between I–V and C–V Characteristics of InGaZnO TFTs Having AIO <sub>x</sub> Gate Insulator Jaehyun Ahn, Seungkyun Ham, and Jaewook Jeong School of Information and Communication Engineering, Chungbuk National University
TP1-100	The Effect of Seed Layer Engineering on the Performance of HZO-Based Ferroelectric Field Effect Transistor (FeFET) JunHyeok Park <sup>1</sup> , Chulwon Chung <sup>2</sup> , Boncheol Ku <sup>1</sup> , Seung Hyeon Yun <sup>1</sup> , Kyungsoo Park <sup>1</sup> , Yu Jeong Choi <sup>1</sup> , and Changhwan Choi <sup>1</sup> <sup>1</sup> Division of Materials Science and Engineering, Hanyang University, <sup>2</sup> Department of Energy Engineering, Hanyang University
TP1-101	8-inch MgO Thin Film Technology for Next-Generation Memory Applications Giryun Hong, Beomjoo Ham, Jongseo Park, Jehyun An, Bohyeon Kang, Sung-min Ahn, and Rock-Hyun Baek Department of Electrical Engineering, POSTECH
TP1-102	Development of ALD Based VO <sub>2</sub> Thin Film FormationProcess Technology and Implementation of Firing Type Threshold Switching Device Yong Tae Kim <sup>1</sup> , Yewon Seo <sup>2</sup> , Pyeongkang Hur <sup>2</sup> , Junwoo Son <sup>2</sup> , and Jaeyeong Heo <sup>1</sup> <sup>1</sup> Chonnam National University, <sup>2</sup> POSTECH
TP1-103	Vertical Side-Wall MoS <sub>2</sub> Channel Transistors : Thicknesses of 0.65nm and 6.5nm Ki Han Kim <sup>1</sup> , Huimin Lee <sup>2</sup> , Joonki Suh <sup>2</sup> , and Byung Chul Jang <sup>1</sup> <sup>1</sup> School of Electronic and Electrical Engineering, Kyungpook National University, <sup>2</sup> Department of Materials Science and Engineering,UNIST



TP1-104	Multiply and Accumulate Operation with 1 Selector 1 RRAM Device 1K Crossbar Arrays June Hyuk Lee, Su Yeon Lee, Hyun Kyu Seo, Se Yeon Jeong, Min Kyung Lee, and Min Kyu Yang Intelligent Electronic Device Lab, Sahmyook University
TP1-105	HfO <sub>x</sub> -Based Synaptic Memristor for Neuromorphic Computing Se Yeon Jeong, Hyun Kyu Seo, Su Yeon Lee, June hyuk Lee, Min Kyung Lee, and Min Kyu Yang Intelligent Electronic Device Lab, Sahmyook University
TP1-106	High Mobility Oxide Thin Film Transistor with Amorphous In-Ga-Sn-O Fabricated by RF-magnetron Sputtering Hyunil Jo <sup>1</sup> , Juhan Kim <sup>1</sup> , Sumi Kim <sup>1</sup> , Eunji Kim <sup>1</sup> , Yugyu Jang <sup>1</sup> , Myeongcheol Jo <sup>1</sup> , Boram Shin <sup>1</sup> , Yiryeong Choi <sup>1</sup> , Joon-Hyung Lee <sup>1</sup> , Byeong-Seong Jeong <sup>2</sup> , and Young- Woo Heo <sup>1</sup> <sup>1</sup> School of Materials Science and Engineering, Kyungpook National University, <sup>2</sup> Department of Hydrogen and Renewable Energy, Kyungpook National University
TP1-107	Methane Gas Detection Sensors based on Carbon Nano Tube Da Gyo Yoo, Kyung Eun Kim, Ryang Ha Kim, and Young Lae Kim Department of Electronic Engineering, Gangneung-Wonju National University
TP1-108	Nitric Oxide Gas Detection and Analysis by Single-walled Carbon Nanotubes-Based Sensor Kyung Eun Kim, Ryang Ha Kim, and Young Lae Kim Gangneung-Wonju National University
TP1-109	Mechanism of Hydrogen-Induced Negative Threshold Voltage Shift in InSnZnO TFT under Positive Bias Temperature Stress Seong-In Cho and Sang-Hee Ko Park KAIST
TP1-110	Non-volatile Behavior in ZrO <sub>2</sub> -Based Ferroelectric-like Memory Devices Using Asymmetric Metal Work-function Engineering SeungHyeon Yun <sup>1</sup> , Chulwon Chung <sup>2</sup> , Boncheol Ku <sup>1</sup> , Junhyeok Park <sup>1</sup> , Kyungsoo Park <sup>1</sup> , Yu Jeong Choi <sup>1</sup> , and Changhwan Choi <sup>1</sup> <sup>1</sup> Division of Materials Science and Engineering, Hanyang University, <sup>2</sup> Deparment of Energy Engineering, Hanyang University

## 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

TP1-111	Improved DRAM Electrode/Dielectric Interface Properties Using $Nb_2O_5$
	and Ta₂O₅ Ultrathin Layer
	Yong ju Kwon, Woo hyuk Kim, and Woo-Hee Kim
	Department of Materials Science and Chemical Engineering, BK <sup>21</sup> FOUR ERICA-ACE
	Center, Hanyang University
	Develop Behavior of Low Temperature Chemical Vapor Deposited Sn-
TP1-112	Based Inorganic Dry Resist for Next-generation EUV Lithography
IP1-112	Hye Kyung Kim and Woo-Hee Kim
	Department of Materials Science and Chemical Engineering, Hanyang University
	Multilevel Switching Behavior in Physically Transient Memristor for
	Biodegradable Electronics
TP1-113	Mohammad Tauquir Alam Shamim Shaikh <sup>1,2</sup> and You Seung Rim <sup>1,2</sup>
	<sup>1</sup> Department of Semiconductor Systems Engineering, Sejong University, <sup>2</sup> Department
	of Intelligent Mechatronics Engineering and Convergence Engineering for Intelligent
	Drone, Sejong University
	Morphology Engineering in Mo-Hf <sub>0.5</sub> Zr <sub>0.5</sub> O <sub>2</sub> -Mo Metal-ferroelectric-metal
	Capacitor with Surface Pre-treatment
TP1-114	Seung Yeon Kim, Dong Hee Han, and Woojin Jeon
171-114	Department of Advanced Materials Engineering for Information and Electronics,
	Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung
	Hee University

F. Silicon and Group-IV Devices and Integration Technology 분과

ZONE 1 (1층 전시장)

TP1-115	<b>수직 적층 실리콘 나노와이어 FBFET의 메모리 특성 연구</b> 류승호 <sup>1</sup> , 조경아 <sup>2</sup> , 김상식 <sup>1.2</sup> <sup>1</sup> 고려대학교 반도체시스템공학과, <sup>2</sup> 고려대학교 전기전자공학과
TP1-116	피드백 전계효과 트랜지스터 기반 링 오실레이터 동작 특성 연구 손재민, 조경아, 김상식 고려대학교 전기전자공학과
TP1-117	나노시트 피드백 전계효과 트랜지스터의 Neural Oscillation 동작 연구 허효주 <sup>1</sup> , 신연우 <sup>1</sup> , 류승호 <sup>2</sup> , 조경아 <sup>1</sup> , 김상식 <sup>1,2</sup> <sup>1</sup> 고려대학교 전기전자공학과, <sup>2</sup> 고려대학교 반도체시스템공학과

TP1-118	Radiofrequency Switches based on Vanadium Oxide Dahyeon Kim <sup>1</sup> , Jiyeon Ryu <sup>2</sup> , Changwoo Pyo <sup>1</sup> , Seung Chan Lee <sup>1</sup> , Tae-Sik Yoon <sup>2,3</sup> , and Myungsoo Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical and Computer Engineering, UNIST, <sup>2</sup> Graduate School of Semiconductor Materials and Devices Engineering, UNIST, <sup>3</sup> Department of Materials Science and Engineering, UNIST
TP1-119	Characterization Si Micro-single Crystals with Chiral Properties Jeongbin Heo <sup>1</sup> , Kyoung Hwa Kim <sup>1</sup> , Suhyun Mun <sup>1</sup> , Seonwoo Park <sup>1</sup> , Hyung Soo Ahn <sup>1</sup> , Jae Hak Lee <sup>1,2</sup> , Min Yang <sup>1</sup> , Young Tea Chun <sup>1</sup> , Sam Nyung Yi <sup>1</sup> , Yeon-Suk Jang <sup>3</sup> , Won Jae Lee <sup>3</sup> , Myeong-Cheol Shin <sup>4</sup> , and Sang-Mo Koo <sup>4</sup> <sup>1</sup> Department of Nano-Semiconductor Engineering, Korea Maritime and Ocean University, <sup>2</sup> LNBS Co., Ltd., <sup>3</sup> Department of Advanced Materials Engineering, Dong- Eui University, <sup>4</sup> Department of Electronic Materials Engineering, Kwangwoon University
TP1-120	HV CMOS 공정에서 인접 소자 영향으로 인한 Parasitic Leakage 개선 강형근, 이도현, 고대현, 황수진, 이문영, 남명희, 박정수 Department of Technology Development, SK hynix system ic
TP1-121	Impact of Work-function Variation in Ferroelectric Field-Effect Transistor Su Yeon Jung and Jang Hyun Kim Department of Intelligence Semiconductor Engineering, Ajou University
TP1-122	Effects of Pre-heating Zone on Dopant Activation by Continuous-wave Laser at High Scan Speed Dong Hyeok Choi <sup>1</sup> , Seung Hwan Kim <sup>1</sup> , Nak Sun Sung <sup>1</sup> , Sung Wook Jang <sup>2</sup> , and Sang Hee Yang <sup>3</sup> <sup>1</sup> Laser Advanced Technology Team, AP Systems Co., Ltd., <sup>2</sup> Laser Equipment Department, AP Systems Co., Ltd., <sup>3</sup> Display Equipment Division, AP Systems Co., Ltd.
TP1-123	메쉬 타입 플로팅게이트를 이용한 시냅스 트랜지스터 제작 정소연 <sup>1</sup> , 양정목 <sup>1</sup> , 김재민 <sup>1</sup> , 채수현 <sup>1</sup> , 구태환 <sup>1</sup> , 장문규 <sup>1,2</sup> <sup>1</sup> School of Nano Convergence Technology, Hallym University, <sup>2</sup> Center of Nano Convergence Technology, Hallym University
TP1-124	금 나노 입자 양자점을 이용한 플래시 메모리 기반 시냅스 단일 소자 전기적 특성 연구 Jae Min Kim <sup>1</sup> , Jeong Mok Yang <sup>1</sup> , So Yeon Jung <sup>1</sup> , Su Hyeon Chae <sup>1</sup> , Tae Hwan Koo <sup>1</sup> , and Moon Gyu Jang <sup>1,2</sup> <sup>1</sup> School of Nano Convergence Technology, Hallym University, <sup>2</sup> Center of Nano Convergence Technology, Hallym University

TP1-125	Large-LRS Vertical ReRAM with Network Semiconductor CNT-Edge Electrodes for Large-scale Array Size Sungmin Eum <sup>1</sup> , Haksoon Jung <sup>2</sup> , Hyunho Gu <sup>1</sup> , and Jimin Kwon <sup>1</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Department of Chemical Engineering, POSTECH
TP1-126	Achieving Both Enhancement-mode Operation and Large On-current in Bottom-gate Indium Tin Oxide Transistors Hyeonho Gu <sup>1</sup> , Haksoon Jung <sup>2</sup> , and Jimin Kwon <sup>1</sup> <sup>1</sup> Department of Electrical-Engineering, UNIST, <sup>2</sup> Department of Chemical Engineering, POSTECH
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TP1-128	Quantitative Analysis on Read/Write Performance in GAAFET-Based 6T- SRAM Bit Cell Changwoo Han <sup>1</sup> , Yejoo Choi <sup>2</sup> , and Changhwan Shin <sup>1</sup> <sup>1</sup> School of Electrical Engineering, College of Engineering, Korea University, <sup>2</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University
TP1-129	밀리미터파 III-V/Si 단일 3차원 (M3D) 집적을 위한 고성능 Si 수동소자 집적 기술 개발 성민경 <sup>1</sup> , 박민식 <sup>2</sup> , 정재용 <sup>3</sup> , 임정택 <sup>4</sup> , 송재혁 <sup>4</sup> , 송종현 <sup>1,4</sup> , 이원철 <sup>1,4</sup> , 심갑섭 <sup>1,4</sup> , 서동주 <sup>1</sup> , 임 유리 <sup>1</sup> , 고형호 <sup>4</sup> , 김철영 <sup>4</sup> , 설우석 <sup>1</sup> , 김상현 <sup>3</sup> , 이종원 <sup>1</sup> <sup>1</sup> 나노종합기술원, <sup>2</sup> 한밭대학교, <sup>3</sup> 한국과학기술원, <sup>4</sup> 충남대학교
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TP1-131	Charge Storage Memory Utilizing Ge Quantum Dots Gyu Bin Lee, Gyeong Min Seo, and Byoung Don Kong Department of Electrical Engineering POSTECH

TP1-132	Impact of RTA on the Way of Forming Filaments in Oxide RRAM Bit Cell Gwon Kim <sup>1</sup> and Changhwan Shin <sup>2</sup> <sup>1</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University, <sup>2</sup> School of Electrical Engineering, Korea University
TP1-133	Optimization of T-CMOS Based Ternary Content-Addressable Memory Cell for High-density Application Jun Young Park <sup>1</sup> , Young-Eun Choi <sup>1</sup> , Woo-Seok Kim <sup>1</sup> , Myoung Kim <sup>1</sup> , Yesong Jeong <sup>1</sup> , Sang Hun Yeo <sup>1</sup> , Kwan Yong Lee <sup>1</sup> , In Jun Jang <sup>1</sup> , Min Woo Ryu <sup>1,2</sup> , Kyung Rok Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Ternell Corp.
TP1-134	Study of Spacer Material Effects on 3D NAND Flash Memory Characteristics in Retention State Yun-Jae Oh <sup>1</sup> , Yunejae Suh <sup>2</sup> , Inyoung Lee <sup>1</sup> , Daewoong Kang <sup>3</sup> , and II Hwan Cho <sup>1</sup> <sup>1</sup> Department of Electronic Engineering, Myongji University, <sup>2</sup> Department of Electronic Engineering, Soongsil University, <sup>3</sup> Department of Next Generation Semiconductor Convergence and Open Sharing System, Seoul National University
TP1-135	Analysis of Interface Trap Density in Metal-Ferroelectric-Insulator - Semiconductor (MFIS) Capacitor with High-k Dielectrics Chankoo Kim <sup>1</sup> , Dong Keun Lee <sup>1</sup> , Seonggeun Kim <sup>1</sup> , Tae-Hyeon Kim <sup>2</sup> , Sihyun Kim <sup>1</sup> , and Sangwan Kim <sup>1</sup> <sup>1</sup> Department of electronic engineering, Sogang university, <sup>2</sup> School of Electrical and Computer Engineering, Georgia Institute of Technology
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TP1-137	Analysis on the Impact of Charge Traps in FeTFET Yun Seo Choi <sup>1</sup> , Seungwon Go <sup>1</sup> , Tae-Hyeon Kim <sup>2</sup> , Sihyun Kim <sup>1</sup> , and Sangwan Kim <sup>1</sup> Department of Electronic Engineering, Sogang University, <sup>2</sup> School of Electrical and Computer Engineering, Georgia Institute of Technology
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TP1-139	Multi-bit Vertical Ferroelectric-Metal Field-Effect Transistor (V-FeMFET) Weight Cell for Neuromorphic Computing Heebum Kang <sup>1</sup> , Seungmin Kang <sup>1</sup> , Tae-Hyeon Kim <sup>2</sup> , Sangwan Kim <sup>1</sup> , and Sihyun Kim <sup>1</sup> <sup>1</sup> Department of Electronic Engineering, Sogang University, <sup>2</sup> School of Electrical and Computer Engineering, Georgia Institute of Technology
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TP1-146	Machine-learning Model to Predict the LER (line-edge-roughness)- induced Random Variation in GAAFET Myongjin Kim and Changhwan Shin Department of Electrical Engineering, Korea University
TP1-147	Analysis of Photoresponse with Asymmetry Ratio for High-performance based on Trantenna Min Jae Kim <sup>1</sup> , Sang Hyo Ahn <sup>1</sup> , Yoo Bin Song <sup>1</sup> , Min Woo Ryu <sup>1,2</sup> , and Kyung Rok Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Ternell Corp
TP1-148	Non-uniform Interface Trap Density by Halo Ion-implantation Process for Flicker Noise Estimation Yoo Bin Song, Sang Hyo Ahn, Min Jae Kim, Min Woo Ryu, and Kyung Rok Kim Department of Electrical Engineering, UNIST
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TP1-157	A Novel Hybrid Ferroelectric Charge Trap Layer Gate-Injection Flash Hyungju Noh, Yelim Jeon, Sihyun Kim, and Sangwan Kim Department of Electrical Engineering, Sogang University
TP1-158	A 28-nm Ternary Dual-Port SRAM Cell for Area and Power Efficient On- chip Memory Myoung Kim <sup>1,2</sup> , Young Eun Choi <sup>1</sup> , Woo-Seok Kim <sup>1</sup> , Yesong Jeong <sup>1</sup> , Jun Young Park <sup>1</sup> , Sang Hun Yeo <sup>1</sup> , Kwan Yong Lee <sup>1</sup> , In Jun Jang <sup>1</sup> , Min Woo Ryu <sup>1,2</sup> , and Kyung Rok Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Ternell Corp.
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TP1-163	TCAD-Based Analysis and Modeling of Process Variations in 28-nm Ternary-CMOS Technology Kwan Yong Lee <sup>1</sup> , Woo-Seok Kim <sup>1</sup> , Young-Eun Choi <sup>1</sup> , Myoung Kim <sup>1,2</sup> , Sang Hun Yeo <sup>1</sup> , Ye song Jeong <sup>1</sup> , Jun Young Park <sup>1</sup> , In Jun Jang <sup>1</sup> , Min Woo Ryu <sup>1,2</sup> , and Kyung Rok Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Ternell Corp.
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TP1-165	Foundry Platform Demonstration of Ternary Logic Circuits by Exploiting Halo Implantation for Ternary-Binary Hybrid System Integration Woo-Seok Kim <sup>1</sup> , Young-Eun Choi <sup>1</sup> , Myoung Kim <sup>1,2</sup> , Sang Hun Yeo <sup>1</sup> , Kwan Yong Lee <sup>1</sup> , In Jun Jang <sup>1</sup> , Jun Young Park <sup>1</sup> , Yesong Jeong <sup>1</sup> , Min Woo Ryu <sup>1,2</sup> , and Kyung Rok Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Ternell Corp.
TP1-166	Highly Scalable Nanosheet Based Ternary-CMOS Technology In jun Jang <sup>1</sup> , Woo-Seok Kim <sup>1</sup> , Young-Eun Choi <sup>1</sup> , Myoung Kim <sup>1</sup> , Sang Hun Yeo <sup>1</sup> , Kwan Yong Lee <sup>1</sup> , Jun Young Park , Yesong Jeong <sup>1</sup> , Min Woo Ryu <sup>1,2</sup> , and Kyung Rok Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Ternell Corp.

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	<sup>1</sup> Department of Electronic and Electrical Engineering, Ewha Womans University,
	<sup>2</sup> Department of Electronics and Electrical Engineering, Dongguk University,
	<sup>3</sup> Department of Electrical and Electronic, and Control Engineering, Hankyoung
	National University
	A Single-Body Integrated Ultra-Low-Power Logic-Memory Cell
	Gyuhoon Lee <sup>1</sup> , Soomin Kim <sup>2</sup> , Yeji Lee <sup>3</sup> , Myounggon Kang <sup>4</sup> , Sungjun Kim <sup>1</sup> , and
	Seongjae Cho <sup>2</sup>
TP1-168	<sup>1</sup> Department of Electronics and Electrical Engineering, Dongguk University,
	<sup>2</sup> Department of Electronic and Electrical Engineering, Ewha Womans University, <sup>3</sup> Department of Electrical and Electronic and Control Engineering, Userlage
	<sup>3</sup> Department of Electrical and Electronic, and Control Engineering, Hankyoung National University, <sup>4</sup> Department of Electronics Engineering, Korea National
	University of Transportation

#### I. MEMS & Sensor Systems 분과

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	Ju Chan Choi, Kwan Soo Kim, Seung Han Ryu, Ji Do Kim, Kwang Woong Jeong, Tae
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	Wafer Level Test에서 Probe Tip의 Contact 압력 및 위치에 따른 MEMS
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TP1-172	Dielectrophoretic Device
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	Department of Biomedical Engineering, Yonsei University
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TP1-174	Nanoporous MoS <sub>2</sub> FET-based Bioelectric Sensor Capable of Highly Selective and Sensitive Detection of Ethanol by Mimicking Drosophila Olfactory System Junoh Shim, Anamika Sen, Heekyeong Park, Arindam Bala, Mincheol Park, and Sunkook Kim Department of Advanced Materials Science and Engineering, Sungkyunkwan University
TP1-175	Effective Detection of BSA with High-performance DG-ISFET and Surface Treated Sensing Membranes Dong-Gyun Mah, Yeong-Ung Kim, and Won-Ju Cho Department of Electronic Materials Engineering, Kwangwoon University
TP1-176	pH-dependent Tunable Sensitivity in Electric-Double-Layer Transistors with Extended-Gate for Neuromorphic Biosensors Dong Hee Lee, Hwi-Su Kim, and Won-Ju Cho Department of Electronic Materials Engineering, Kwangwoon University
TP1-177	Nano-physical Unclonable Function Created by Nanopatterns from Block Copolymer Self-assembly Hyeon Ju Ko, Jang Hwan Kim, and Sang Ouk Kim Department of Material Science & Engineering, KAIST
TP1-178	High-current, Large-area Organic Photovoltaics for Indoor Applications Jooyeong Kim <sup>1</sup> , Hyojeong Choi <sup>2</sup> , Selim Han <sup>2</sup> , Biswas Swarup <sup>2</sup> , and Hyeok Kim <sup>2</sup> <sup>1</sup> Dept. of Intelligent Semiconductor Engineering, University of Seoul, <sup>2</sup> School of Electrical and Computer Engineering, University of Seoul
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TP1-189	Effect of Forming Gas Annealing on Reliability of Embedded Poly-silicon Micro-heater Jinwoo Park, Gyuweon Jung, Wonjun Shin, Chayoung Lee, Donghee Kim, Kangwook Choi, Hunhee Shin, Min-Kyu Park, Joon Hwang, Jae-Joon Kim, and Jong-Ho Lee Department of Electrical and Computer Engineering and ISRC Seoul National University
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TP1-192	인체부착형 마찰전기 기반 움직임 감지 센서 한윤승 <sup>1</sup> , 윤홍준 <sup>2</sup> , 박윤석 <sup>1</sup> <sup>1</sup> 경희대학교 정보전자신소재공학과, <sup>2</sup> 가천대학교 전자공학부
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TP1-194	Thermally Managed Composites Assisted Wireless Body Temperature Sensor Doyoung Kim and Sang Min Won Department of Electrical and Computer Engineering, Sungkyunkwan University
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TP1-198	IZO/ZnO Nanowire Heterostructure for Enhanced Biomolecule Sensing Performance of Heterostructure-Based TFT June Soo Kim, Jae Yong Lee, Seung Deok Kim, Da Ye Kim, Hyunjun Kim, Noah Jang, Jiajie Wang, Yujin Nam, Jinkyung Kim, Maeum Han, and Seong Ho Kong School of Electronics and Electrical Engineering, Kyungpook National University
TP1-199	Nanostructured Zinc Oxide Thin Film : An Innovative pH Sensing Solution Noah Jang, June Soo Kim, Maeum Han, Seung Deok Kim, Jae Yong Lee, Jiajie Wang, Hyunjun Kim, Da Ye Kim, Yujin Nam, Jinkyung Kim, and Seong Ho Kong School of Electronic and Electrical Engineering Kyungpook National University
TP1-202	SPAD-Based LiDAR Sensor with Adaptive Power Saving Scheme Dahwan Park <sup>1</sup> , Eun-chang Lee <sup>1</sup> , Min-Kyu Kim <sup>1</sup> , Sang-Young Lee <sup>1</sup> , Yong-Seop Lee <sup>1</sup> , Min-Seok Shin <sup>1</sup> , and Hoesam Jeong <sup>1</sup> SK hynix
TP1-203	A Smart Ring for Real-Time Blood Pressure Monitoring Junyeong Lee, Minjoo Lee, and Jeonghyun Kim Department of Electronic Convergence Engineering, Kwangwoon University
TP1-204	Non-Invasive Real-Time Blood Glucose Monitoring for Reducing Variations in Diabetes Care Seongu Kim and Jeonghyun Kim Department of Electronic Convergence Engineering, Kwangwoon University
TP1-205	Integration of Semiconductor Components Using 3D Stacking Technology and Sensory-Neuromorphic Application Se Gi Lee and Sang Min Won Sungkyunkwan University

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TP1-206	Application of Innovative Wiring Method of In-vivo Experiments Janghoon Joo and Sang Min Won Sungkyunkwan University
TP1-207	Flexible Artificial Tactile System Using Morphotropic Phase Boundary of Hf <sub>x</sub> Zr <sub>1-x</sub> O <sub>2</sub> Thin Film by Low-Temperature Annealing Seungyeob Kim, Minhyun Jung, Jinwook Ha, and Sanghun Jeon School of Electrical Engineering, KAIST
TP1-208	단일 벽 탄소 나노튜브를 이용한 황화수소 가스 센서의 제작과 검출 Ryang Ha Kim, Kyung Eun Kim, Beom Jun Jung, and Young Lae Kim Electronic Engineering, Gangneung-Wonju National University
TP1-209	Wireless, Battery Free Temperature Sensor based on Morphotropic Phase Boundary of Hf <sub>x</sub> Zr <sub>1-x</sub> O <sub>2</sub> Thin Film Ketong Yang, Seungyeob Kim, Minhyun Jung, and Sanghun Jeon KAIST
TP1-210	In-Situ Electron Density Measurement in Inductively Coupled Plasma Using Microwave Reflectometer by Wi-Fi Antenna on Wafer Seong-Yong Lim, Gi-Won Shin, Woo-Jae Kim, Hee-Tae Kwon, Ji-Hwan Kim, In-Young Bang, Jae-Hyeon Kim, Hyeon-Jo Kim, Seong-Hee Cho, Seo-Yeon Kim, and Gi-Chung Kwon Department of Electrical and Biological Physics, Kwangwoon University
TP1-211	P-Type Copper Oxide-Based Solar-blind Ultraviolet (UV) Photodetector Capable of Low-PhotocurrentOperation with Plasma-Enhanced Atomic Layer Deposition (PEALD) Minah Park <sup>1</sup> , Jaewook Yoo <sup>1</sup> , Hyeonjun Song <sup>1</sup> , Soyeon Kim <sup>1</sup> , Hongseung Lee <sup>1</sup> , Seongbin Lim <sup>1</sup> ,Seohyeon Park <sup>1</sup> , Peide D. Ye <sup>2</sup> , and Hagyoul Bae <sup>1</sup> <sup>1</sup> Jeonbuk National University, <sup>2</sup> Purdue University
0. System LSI	5
	ZONE 1 (1층 전시장)

TP1-212 Two-step Classification Neuron Circuits for Highly Integrated SNN Systems Dahyeon Youn and Soo Youn Kim Department of Semiconductor Science, Dongguk University

TP1-213	An Automatic Salt-water-spray Roadway-deicing System with Surface Detection Ki-Duk Kim <sup>1</sup> and Hyung-Min Lee <sup>2</sup> <sup>1</sup> C&Tech Co., Ltd., <sup>2</sup> Korea University
TP1-214	Aggregator Hardware Design for Preventing Backdoor Attacks in Federated Learning YeJi Lee, JoonSeok Kim, KyuMin Cho, and SeokHyung Kang Department of Electrical Engineering, POSTECH
TP1-215	50G-PON 용 LDPC 부호기 FPGA 구현         최정원 <sup>1</sup> , 김광옥 <sup>2</sup> , 두경환 <sup>2</sup> , 정환석 <sup>2</sup> , 이영주 <sup>1</sup> <sup>1</sup> 포항공과대학교 전자전기공학과, <sup>2</sup> 한국전자통신연구원 입체통신연구소 네트워크연구본부         광네트워크연구실
TP1-216	HDL Code Coverage Verification Method 엄유진, 양희훈, 김도훈, 유호영 충남대학교 전자공학과
TP1-217	GPS CRC-24Q 디코더 구현 황용택, 황지우, 유호영 충남대학교 전자공학과
TP1-218	노외중성자속 감시계통 검증을 위한 FPGA 신호생성기 개발 신건, 양희훈, 박요한, 노윤진, 유호영 충남대학교 전자공학과
TP1-219	링 오실레이터 인버터 수에 따른 PUF 성능 분석 박지호, 양희훈, 유호영 충남대학교 전자공학과
TP1-220	Verification Methodology for Rate Control Unit in VDC-M Decoder Jiyoung Lee, Huijin Roh, Sohyeon Kim, Saeyeon Kim, Hannah Yang, and Ji-Hoon Kim Department of Electronic and Electrical Engineering, Ewha Womans University

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TP1-221	Multi-Stage Rate Control Architecture for VDC-M Decoder Huijin Roh, Jiyoung Lee, Sohyeon Kim, Saeyeon Kim, Hannah Yang, and Ji-Hoon Kim Department of Electronic and Electrical Engineering, Ewha Womans University
TP1-222	Design of Custom DRAM Memory Controller for ALPG Testing Seoyeon Park, Saeyeon Kim, Eunkyung Ham, Sunyoung Park, and Ji-Hoon Kim Department of Electronic and Electrical Engineering, Ewha Womans University

#### Q. Metrology, Inspection, Analysis, and Yield Enhancement 분과

ZONE 3 (2층 로비)

TP1-223	비 균일 격자 마크를 이용한 라지 오버레이 문제 개선 방법 Hyun Chul Lee <sup>1,3</sup> , Hyun Jin Chang <sup>1</sup> , Ho Sung Woo <sup>2</sup> , and Won Gyu Lee <sup>3</sup> <sup>1</sup> AUROS Technology, Inc., <sup>2</sup> Korea National Open University, <sup>3</sup> Korea University
TP1-224	Power Spectral Density Analysis for SEM Line Pattern Roughness Ra Seong Ki <sup>1</sup> , Jong Hoi Cho <sup>1</sup> , Sung Hun Lim <sup>1</sup> , Jun Ho Lee <sup>1</sup> , Hyun Jin Lee <sup>1</sup> , Ran Alkoken <sup>2</sup> , You Jin Kim <sup>2</sup> , Jeong Ho Yeo <sup>2</sup> , Jung Woo Sung <sup>3</sup> , Kyung Ju Han <sup>3</sup> , and Kyu Young Kim <sup>1</sup> <sup>1</sup> SK hynix, <sup>2</sup> PDC business group, Applied Materials, Israel, <sup>3</sup> PDC business group, Applied Materials, Korea
TP1-225	FourierTransformInfraredSpectroscopy(FTIR)inCharacterizingBorophosphosilicateGlass(BPSG)MinYoung LeeSemilab Korea Co., Ltd.
TP1-226	Development of Dual-rotating Polarizer Spectroscopic Ellipsometry Jongkyoon Park, Sukhyun Choi, Yong Jai Cho, Junho Choi, and Chegal Won Division of Advanced Instrumentation Institute, KRISS
TP1-227	CMOS Image Sensors의 암 전류를 감소시키는 Shallow Trench Isolation(STI) Sac Oxide Process Module 적용 Cheoleon Park, Jea Young Park, Ki Young Kim, Sun Choi, and Won Ho Lee R&D Division, SK hynix system ic
TP1-228	Determination of Outdoor Airborne Nano-particle Impact on Defect by Development of New Data Processing Algorithm Jongmin Lee <sup>1,2</sup> , Jungtae Park <sup>1,2</sup> , II-Jin Kim <sup>2</sup> , Haeun Lee <sup>2</sup> , and Sehoon Park <sup>2</sup> <sup>1</sup> Department of Materials Science & Engineering, Yonsei University, <sup>2</sup> Samsung Electronics Co., Ltd.

TP1-229	CIS (CMOS Image Sensor) BSI 제품 ML (Micro Lens) Stripe Defect 개선 방법 Joo Young Jeong, Ki Young Kim, Han Yi Jin, Sun Choi, and Won Ho Lee R&D Division, SK hynix system ic
TP1-230	Real-time 3D Surface Reconstruction of Deflectometry Using Deep Learning In-Kyu Park <sup>1,2</sup> , Young-Sik Ghim <sup>1,2</sup> , and Hyug-Gyo Rhee <sup>1,2</sup> <sup>1</sup> KRISS, <sup>2</sup> Department of Precision Measurement, UST
TP1-231	In-depthDOSProfilesinSolution-processedIZOSemiconductorDependingontheInDopingUsingPhotocurrentSpectroscopyDongwook Kim <sup>1</sup> , Hyeonju Lee <sup>1</sup> , Soo-Kyoung Cha <sup>2</sup> , Chanho Jeong <sup>2</sup> , Youngjun Yun <sup>2</sup> ,and Jaehoon Park <sup>2</sup> <sup>1</sup> School of Information Science, Hallym University, <sup>2</sup> School of Semiconductor DisplayTechnology, Hallym University
TP1-232	Contact Holes in Vertical Electrode Structures Analyzed by GISAXS Gyungtae Kim <sup>1</sup> , Tae Gun Kim <sup>1</sup> , Young Jun Chang <sup>2</sup> , and Young Yong Kim <sup>3</sup> <sup>1</sup> National Nanofab Center, <sup>2</sup> University of Seoul, <sup>3</sup> Pohang Accelerator Laboratory
TP1-233	Physically Unclonable Functions via Disordered Heteronanostructure of 2D Semiconducting Material: Enhancing Entropy and Parameter Space Jaeseo Park <sup>1</sup> , Jun Oh Kim <sup>1</sup> , Won Chegal <sup>1</sup> , and Sang-Woo Kang <sup>1,2</sup> <sup>1</sup> Advanced Instrumentation Institute, KRISS, <sup>2</sup> Precision Measurement, UST
TP1-234	Enhancement of Electrical Properties in MOCVD-Grown MoS <sub>2</sub> -Based Field-Effect Transistors: A Comparative Study of Contact Strategies Junghyun Lee <sup>1,2</sup> , Jaeseo Park <sup>1</sup> , Hyeonji Kim <sup>1,3</sup> , Bongjoong Kim <sup>2</sup> , Sang-Woo Kang <sup>1,4</sup> , and Jun Oh Kim <sup>1</sup> <sup>1</sup> KRISS, <sup>2</sup> Hongik University, <sup>3</sup> Kyungpook National University, <sup>4</sup> UST
TP1-235	EUV 펠리클에 포집된 임계 크기의 입자가 마스크 이미지 전사특성에 미치는         영향에 대한 실험적 연구         문승찬 <sup>1,3</sup> , 이동기 <sup>2,3</sup> , 홍준호 <sup>2,3</sup> , 안진호 <sup>1,2,3</sup> <sup>1</sup> 한양대학교 나노반도체공학과, <sup>2</sup> 한양대학교 신소재공학과, <sup>3</sup> EUV-IUCC

TP1-236	Parameter Optimization for Precision Improvement in Thickness Measured with Spectroscopic Ellipsometry
	Inhee Joh, Seojin Park, Myeongrok Oh, Hwanseong Moon, Mita Park, Kyusik Kim, and Tae Dong Kang AUROS Technology, Inc.
	Imaging Spectroscopic Ellipsometer based on One-piece Polarizing Interferometer: Characterization of the 2D Van Der Waals Materials
TP1-237	Suk Hyun Choi <sup>1,2</sup> , Guk Hyeon Hwang <sup>1</sup> , Saeid Kheiryzadehkhanghah <sup>1</sup> , Yong Jai Cho <sup>2</sup> , Junho Choi <sup>2</sup> , Jongkyoon Park <sup>2</sup> , Won Chegal <sup>2</sup> , and Dae Suk Kim <sup>1</sup>
	Optical Simulation of Measurement Sensitivity on Critical Dimension of
TP1-238	Cu Micro-bumps for Semiconductor Packaging Process Shinyoung Ryu <sup>1</sup> , Jiwon Lee <sup>1</sup> , Minhyeok Lee <sup>1</sup> , Kwangwoo Kim <sup>2</sup> , Jongjeong Kim <sup>2</sup> , and Tae Dong Kang <sup>1</sup> <sup>1</sup> AUROS Technology, Inc., <sup>2</sup> Haedosa, Inc.
	Development of High Precision Micro-ellipsometer Enhanced by
TP1-239	<b>Pixelated Polarizing Camera</b> Dong-Geun Yang <sup>1,2</sup> , Young-Sik Ghim <sup>1,2</sup> , and Hyug-Gyo Rhee <sup>1,2</sup> <sup>1</sup> Optical Imaging and Metrology Team, KRISS, <sup>2</sup> Department of Measurement Engineering, UST
TP1-240	반사형 대물렌즈를 이용한 분광 타원계측기 편광상태 변화 보정 서선일 , 주기남 조선대학교
TP1-241	고분해능 3차원 패턴 조사 현미경 조민서, 박종규, 주기남 조선대학교
TP1-242	In-situ Liquid Cell TEM Study for Water Splitting Using Mesoporous Graphitic Carbon Nitride Hetero-structures V. Navakoteswara Rao, Jung Ho Yoo, and Jun-Mo Yang Nano-convergence Technology Division, National Nanofab Center, KAIST



TP1-243	Reverse Engineering Case Study Using Atomic Layer Ion Beam Delayer Jon Won Koh, Myung Keun Lee, Seung Joon Cha, and Yun Chang Park NNFC
TP1-244	터보분자펌프 성능 평가 지표의 신뢰성 향상을 위한 계측기 보정 및 분산 데이         터의 통계학적 프로세싱 방법에 관한 연구         민병현 <sup>1,3</sup> , 임성규 <sup>2</sup> , 문지훈 <sup>1</sup> , 강상우 <sup>1,3</sup> <sup>1</sup> 한국표준과학연구원 첨단측정장비연구소, <sup>2</sup> 나노종합기술연구원 나노공정기술부, <sup>3</sup> 과학기술         연합대학원대학교 정밀측정전공
TP1-245	벽면 오염에 따른 식각 드리프트 제어 운전 알고리즘 개발 이인규, 유상원, 권지원, 박지훈, 김곤호 서울대학교 공과대학 에너지시스템공학부
TP1-246	TLB Coalescing Using Page Table Compression Tran Dai Duong and Jae Young Hur Department of Electronic Engineering, Jeju National University
TP1-247	점진적 패리티로 대용량 NAND Flash Memory의 Open Block 문제 완화 Min-Jin Oh <sup>1</sup> and Jaeho Kim <sup>1,2</sup> <sup>1</sup> School of Aerospace and Software Engineering, Gyeongsang National University, <sup>2</sup> Department of Al Convergence Engineering, Gyeongsang National University
TP1-248	Deep Learning Computation Acceleration through Automatic Tuning of Execution Code Yongin Kwon <sup>1,2</sup> <sup>1</sup> ETRI, <sup>2</sup> UST
TP1-249	ZNS SSD의 자원 경쟁 분석 Gyupin Moon and Donghyun Kang Gachon University
TP1-250	Improved Mobile Application Performance through Database Redesign Jung Kyu Park <sup>1</sup> , and Eun Young Park <sup>2</sup> <sup>1</sup> Changshin University, <sup>2</sup> Shinhan University

TP1-251	PoP-Cache: Hit ratio예측과 사전 퇴출에 의한 캐시 교체 정책의 성능 향상 Hyemi Jeong <sup>1</sup> , Kyeongmin Kim <sup>1</sup> , and Jeaho Kim <sup>1,2</sup> <sup>1</sup> School of Aerospace and Software Engineering, Gyeongsang National University, <sup>2</sup> Department of Al Convergence Engineering, Gyeongsang National University,
S. Chip Desigr	n Contest 분과 ZONE 1 (1층 전시장)
TP1-252	An Arbitrary-Waveform-Capable Neural Stimulator in Standard CMOS Jeongyoon Wie and Junghyup Lee Electrical Engineering and Computer Science, DGIST
TP1-253	A Pulse Counting Digital FOCV-based 41ms Fast Startup Compact Boost Converter for TEG in 28 nm CMOS Seong-Yeon Moon, R. M. I. U. Rajapaksha, and Jong-Wook Lee Department of Electronics and Information Convergence Engineering, Kyung Hee University
TP1-254	Object Tracking Lensless Light Field Image Sensor through a Parallel Bank of Pulse Computational Blocks and Post DNN Using Robot Arm- based Data Collection Sang Hoon Hong, Eon Gyeong Lee, and Han Joon Kim Kyung Hee University
TP1-255	Wide Bandwidth Continuous-time Noise Shaping SAR ADC Sein Oh, Gichan Yun, and Minkyu Je School of Electrical Engineering, KAIST
TP1-256	Wide Bandwidth and High PSR Capacitorless LDO Regulator based on Flipped-voltage Follower Jaerim Baek, Daejeong Kim, and Hyun sun Mo Kookmin University
TP1-257	Design of a Phase-locked Loop with Improved Jitter Performance Using Phase-lock Detector Young Hun Kim, Dae Jeong Kim, and Hyun Sun Mo Kookmin University

TP1-258	A 1.4-8 Gb/s Low Power Quarter-rate Single-loop Reference-less Clock and Data Recovery Circuit with Unlimited Capture Range Jin-Ho Kim, Yujin Na, and Jin-Ku Kang Department of Electrical and Computer Engineering, Inha University
TP1-259	부채널 신호 분석을 위한 하드웨어 백도어 IC 칩 설계 Sun Bhin Kim, Jun Hui Nam, and Dong Kyue Kim Department of Electronics Engineering, Hanyang University
TP1-260	Power Management IC for Supercapacitor Applications Donghyun Kim, Jaehyeong Lee, Jinwoo Oh, Seungyeon Lee, Jeonghee Jeon, and Joongho Choi University of Seoul
TP1-261	Portable Functional Brain Imaging Chip for Frequency-Domain NIRS Method Bumjun Koh, Kyeongha Kwon, and Hyeon-Min Bae KAIST
TP1-262	A Mobile 3D-CNN Processor with Dual-Grained Sparsity-Aware Computation Utilizing Inter-Frame Variation Seungbin Kim, Hoichang Jeong, Wuyoung Jang, Keonhee Park, Bokyoung Seo, Jueun Jung, and Kyuho Lee UNIST
TP1-263	A 8GHz Delay Locked Loop with 16 Multi-phases in 65nm CMOS for BOST Skew Compensation Jinsoo Bae, Jongchan An, Gwangmyeong An, Hyunsu Jang, Taeho Kim, Myeongju Park, Yoonsang Lee, Songi Cheon, Hyanghee Park, Yunseo Song, and Junyoung Song Department of Electronics Engineering, Incheon National University
TP1-264	Buck Converter for Driving GaN Switches Ji Ho Moon, Byeong Ik Kim, and Jeong Jin Roh Hanyang University
TP1-265	Dual-band CMOS Down-conversion Mixer for 5G NR FR2 Applications Eunsoo Kim, Segyeong Kim, Gyuwon Kim, and Junghwan Han Chungnam National University

TP1-266	A Temperature Insensitive 4GS/s 7-bit Time-domain ADC Using Replica Feedback Loop Gyuchan Cho and Jintae Kim Konkuk University
TP1-267	Binary Neural Networks Using Nanoelectromechanical Memory Switches Geun Tae Park <sup>1,2</sup> and Woo Young Choi <sup>1,2</sup> <sup>1</sup> Department of Electrical and Computer Engineering, Seoul National University, <sup>2</sup> ISRC, Seoul National University
TP1-268	Switching Voltage Analysis of Nanoelectromechanical Memory Switches Jin Wook Lee <sup>1,2</sup> and Woo Young Choi <sup>1,2</sup> <sup>1</sup> Department of Electrical and Computer Engineering, Seoul National University, <sup>2</sup> ISRC, Seoul National University
TP1-269	Energy-efficient Computing-in-memory Based System-on-chip Controlled by RISC-V Processor Jihoon Park <sup>1</sup> , Hyunmyung Oh <sup>2</sup> , Jehun Lee <sup>1</sup> , Jaeyong Jang <sup>1</sup> , Sanghyeok Han <sup>1</sup> , and Jae-Joon Kim <sup>1</sup> <sup>1</sup> Seoul National University, <sup>2</sup> POSTECH
TP1-270	Upper-mid Band 6G향 커플러 기반 차동 신호 보상 기법이 적용된 전압제어 발진기 소형화 연구 윤태영 <sup>1,2</sup> , 오정석 <sup>1,2</sup> <sup>1</sup> 서울대학교 전기정보공학부, <sup>2</sup> 서울대학교 뉴미디어통신공동연구소
TP1-271	Seamless Noise Buck-boost Converter with Continuous Input/Output Current Seokhee Han, Jaewon Ryu, and Chulwoo Kim Department of Electrical Engineering, Korea University
TP1-272	Efficient CNN Accelerator: Enabling Inference and Training Geonhui Jang, SangBo Park, GiTae Park, Thaising Taing, Bogeun Jung, and Hyungwon Kim Chungbuk National University
TP1-273	A 4-GS/s 6-bit PVT-Variation Tolerant Time-Domain ADC with Delay Locked Loop Doona Song, Gyuchan Cho, and Jintae Kim Konkuk University

TP1-274	Triple-stacked Distributed Amplifiers Using CMOS 28 nm Process Hosung Kang, Cheonsang Song, and Jihoon Kim Kyonggi University
TP1-275	Area Efficient DAC with Switched Capacitor Amplifier Scheme for AMOLED Source Driver IC Min-Woo Kim, Sang-Min Lee, Yu-Guan Kim, Won-Jo Lee, Yun-Su Kim, and Byung-do Yang Department of Electronics Engineering, Chungbuk National University
TP1-276	A D-band Low Noise Amplifier based on 28-nm CMOS Technology Wooyong Keum, Jaeman Lee, Giyeong Nam, Jaewon Jang, Minsuk Choi, and Jae- Sung Rieh School of Electrical Engineering, Korea University
TP1-277	180nm 공정을 사용한 최대 1.6A의 전류를 구동할 수 있는 다상 통합 전압 레귤레이터 설계 김기원, 김경민, 정현준, 김소영 성균관대학교 정보통신대학
TP1-278	A Single-TL, Simultaneous, Bi-directional, Skew-compensated and Multi-access Transceiver Link System Seong-Min Ko, Jun-Hyeok Park, and Dong-Woo Jee Ajou University
TP1-279	시스템 EMI 노이즈 분석을 위한 On-chip Embedded 오실로스코프의 설계 Kyung Hoon Lee and Jin Gook Kim UNIST
TP1-280	LR-SoC: A Lightweight RISC-V SoC Min Young Lee <sup>1</sup> , Soo Min Rho <sup>1</sup> , Chan Hoon Kim <sup>1</sup> , Dae Eun Wi <sup>1</sup> , Sang Soo Park <sup>2</sup> , and Ki-Seok Chung <sup>1</sup> <sup>1</sup> Hanyang University, <sup>2</sup> Device Solutions, Samsung Electronics Co., Ltd.
TP1-281	다중 분할 병렬 결합 변압기를 사용한 5G 고효율 전력증폭기 설계 김근태, 오규택, 유상진, 이옥구 부산대학교 전기전자공학과



TP1-282	Highly Sensitive Plasmonic Terahertz Detector with Integrated Sub- wavelength Aperture based on Trantenna Min Jae Kim <sup>1</sup> , Sang Hyo Ahn <sup>1</sup> , Yoo Bin Song <sup>1</sup> , Min Woo Ryu <sup>1,2</sup> , and Kyung Rok Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Ternell Corp.
TP1-283	저전력 37uW 10-bit 모노토닉 축차비교형 아날로그-디지털 변환기 신솔몬 <sup>1</sup> , 최예광 <sup>1</sup> , 권미정 <sup>1</sup> , 박유현 <sup>1</sup> , 이원제 <sup>2</sup> , 장성민 <sup>2</sup> , 김영식 <sup>1</sup> <sup>1</sup> 한동대학교 전산전자공학부, <sup>2</sup> 한동대학교 전산전자공학과
TP1-284	A 28-Gb/s ISI-Resistant Digital CDR with Extended Pattern Utilization Suil Kang and Kwanseo Park Yonsei University
TP1-285	A 57-66 GHz Up-converter in 65-nm CMOS for WiGig Applications Geon Woo Park, Jin Man Myung, Ho Kim, Seungjik Lee, and Ilku Nam Pusan National University
TP1-286	Two-stage Operational Transconductance Amplifier with Controllable Reference Voltage Jiwon Lee and Byoungho Kim Hanyang University
TP1-287	저전력 센서 어플리케이션을 위한 Glitch-free 포스트 디바이더를 포함한 광대 역 주파수 생성기 정상돈, 전정훈 Department of Semiconductor and Display Engineering, Sungkyunkwan University
TP1-288	A 230-GHz ×12 Frequency Multiplier Chain in 250-nm InP HBT Technology Giyeong Nam, Wooyong Keum, Jaeman Lee, Jaewon Jang, Minseok Choi, Myeongjae Kim, and Jae Sung Rieh School of Electrical Engineering, Korea University
TP1-289	Electromagnetic Analysis Countermeasure Circuit for AES Crypto Module Dongmin Lee and Byong-Deok Choi Dept. of Electronic Engineering, Hanyang University



TP1-290	교차 쌍대의 증폭 구조를 활용한 소형화된 Upper-mid 대역 이득 가변 가능한 능동형 양방향 위상천이기 박의찬 <sup>1,2</sup> , 오정석 <sup>1,2</sup> <sup>1</sup> 서울대학교 전기정보공학부, <sup>2</sup> 서울대학교 뉴미디어통신공동연구소
TP1-291	실시간 저면적 BDS B1C 수신기 구현 황용택, 황지우, 이유석, 유호영 충남대학교 전자공학과
TP1-292	A Low Power and Compact 12bit 17MS/s SAR-ADC with Dual-Split Capacitor DAC Taell Hwang, Malik Summair Asghar, and HyungWon Kim Department of Electronic Engineering, Chungbuk National University
TP1-293	A Low-Power, Low-Noise 3rd-Order Delta-Sigma ADC Using an Inverter- Based Pseudo-Pseudo Differential Integrator Dong-Jick Kim and Jae Hoon Shim Kyungpook National University
TP1-294	A Bandwidth and Resolution Reconfigurable Noise-Shaping SAR ADC for PIM Applications Dongwook Kim, Donggu choi, Junghyup Lee, and Jong-hyeok Yoon DGIST
TP1-295	Charge Sharing Based Computation-In-Memory for Energy Efficient Machine Learning Algorithm Jaehyeon Woo <sup>1</sup> , Dongho Kim <sup>1</sup> , Seokhun Kim <sup>1</sup> , Hongwon Kim <sup>1</sup> , Taesung Kim <sup>1</sup> , Sangheon Lee <sup>1</sup> , Junseo Lee <sup>1</sup> , Jihwan Park <sup>1</sup> , Inseong Jeon <sup>1</sup> , Ijun Jang <sup>1</sup> , Jisu Kang <sup>1</sup> , Jaeseung Baik <sup>1</sup> , and Hanwool Jeong <sup>1,2</sup> <sup>1</sup> Kwangwoon University, Republic of Korea, <sup>2</sup> Articron Inc.
TP1-296	Efficient Pillar-Based 3D Object Detection Accelerator Minjae Lee, Dowon Kim, and Jungwook Choi Hanyang University
TP1-297	A 7-Bit 32x Time-Interleaved SAR ADC with 2-Then-1-Bit/Cycle Conversion Kyungmin Lee, Jonghyun Kim, and Hyungil Chae Konkuk University

TP1-298	Low-voltage Charge Pump based on Internal Gate-bias Boosting for Energy Harvesting Systems So-Bin Lee and Ickjin Kwon Department of Electrical and Computer Engineering, Ajou University
TP1-299	A Low-Power IR-UWB CMOS Transmitter for Energy Harvesting Application Dong-Won Lee and Ickjin Kwon Department of Electrical and Computer Engineering, Ajou University
TP1-300	A Scalable Dual-chip Neural Interface System Joonyoung Lim, Chae-Eun Lee, Chieun Choi, and Yoon-Kyu Song Graduate School of Convergence Science and Technology, Seoul National University
TP1-301	A Low-power 8-b 500MS/s Loop-unrolled SAR ADC with Comparator Offset Calibration Seunghyun Kim and Minjae Lee School of Electrical Engineering and Computer Science, GIST
TP1-302	A 500-kSPS Split-SAR ADC for Foreground Calibration Myeong Gyu Gil <sup>1</sup> and Byoung Ho Kim <sup>1</sup> Hanyang University
TP1-303	A Wideband LO Generator for 5G FR1 Using a Single LC-VCO-Based SSPLL and a Ring-VCO-Based Fractional-Resolution Frequency Multiplier Yongwoo Jo <sup>1</sup> , Juyeop Kim <sup>1</sup> , Yuhwan Shin <sup>1</sup> , and Jaehyouk Choi <sup>2</sup> <sup>1</sup> KAIST, <sup>2</sup> Seoul National University
T. AI 분과	ZONE 1 (1층 전시장)
TP1-304	Dedicated Processing Engines for Depth-wise Separable Convolution Hyeon Seok Hong <sup>1,2</sup> and Hyun Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical and Information Engineering, Seoul National University of Science and Technology, <sup>2</sup> Research Center for Electrical and Information Technology, Seoul National University of Science and Technology

TP1-305	SRAM-Based Near-Memory Computing for Accelerators for Efficient and Accurate Floating Point Computations Myeong Eun Kwon, Je Hun Lee, and Jae-Joon Kim Seoul National University
TP1-306	웨이블릿 계수 분포를 활용한 Fast Domain Generalization Jin Shin <sup>1,2</sup> and Hyun Kim <sup>1,2</sup> <sup>1</sup> Department of Electrical and Information Engineering, Seoul National University of Science and Technology, <sup>2</sup> Research Center for Electrical and Information Technology, Seoul National University of Science and Technology
TP1-307	정확하고 효율적인 부동소수점 행렬-곱 연산을 위한 정수 기반 이상치 인지 시 스톨릭 배열 뉴럴 네트워크 가속기 Jehun Lee and Jae-Joon Kim Seoul National University
TP1-308	A CNN Accelerator based on 3D NAND Flash Memory with Input Reuse In-Seok Lee, Jae-Joon Kim, and Jong-Ho Lee Department of Electrical and Computer, Seoul National University
TP1-309	Analog 기반 Triplet-Based STDP 학습 알고리즘 On-chip Learning 구조 설계 계 Hyeon-Seong Im and Jung-Hoon Chun Department of Semiconductor and Display Engineering, Sungkyunkwan University
TP1-310	Neural Network Framework - SW Architecture and Implementation for a Hardware Accelerator for Deep Reinforcement Learning Dohyun Kim, Junghwan Choi, and Shiho Kim <sup>1</sup> School of Integrated Technology, Yonsei University, <sup>2</sup> BK21 Graduate Program in Intelligent Semiconductor, Yonsei University
TP1-311	플래시 메모리 기반의 SNN 인공지능칩 연구 이왕주, 이성현, 김진하, 김상훈, 박정우, 박민아, 정순규, 손민균, 서동우 한국전자통신연구원



TP1-312	Optimizing Cu-CMP via Deep Learning to Predict Polyurethane Pad Durability
	Seunghwan Lee <sup>1</sup> , Jaewon Lee <sup>1</sup> , Pengzhan Liu <sup>1</sup> , Sanghuck Jeon <sup>1</sup> , and Taesung Kim <sup>1,2</sup> <sup>1</sup> School of Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> SKKU Advanced Institute of Nano Technology, Sungkyunkwan University
	Highly Linear Charge Trap/Detrap of Charge Trap FET Using Regulated
	Pulse
TP1-313	Jeong-In Choi and Kee-Won Kwon
	Department of Electrical and Computer Engineering, Sungkyunkwan University
	Training-Aware Fixed-Point Simulation for Deep Learning Model
TP1-314	Seung Hwan Yoon and Young Ho Seo Kwangwoon University
	Effects of Nonlinear Conductance Update of Synaptic Devices on On-
TP1-315	Chip Learning in Hardware Neural Network
IF 1-515	Seung Whan Kim, Jae-Joon Kim, and Jong-Ho Lee
	Seoul National University
	CNN Preprocessing Based Embedded AI Strawberry Classifier
TP1-316	Jinyeol Kim, Jongwon Oh, Joungmin Park, and Seung Eun Lee
	Department of Electronic Engineering, Seoul National University of Science and Technology
	keti.re.kr Neural Network Accelerator with Quantization for Edge
TP1-317	Computing
	Ji Hun Joe, Min Geon Shin, Han Ul Ryu, and Sung Ho Lee
	KETI
U. Bio-Medica	
	ZONE 1 (1층 전시장)
TP1-318	Granular Adhesive for Injection-on-skin Interface
	Jaepyo Jang <sup>1</sup> , Sungjun Yoon <sup>2</sup> , and Donghee Son <sup>1,2</sup>
	<sup>1</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University,
	<sup>2</sup> Department of Artificial Intelligence System Engineering, Sungkyunkwan University



TP1-319	Enhanced Sensitivity of Si BioFETs with Ag Nanowire for CHIKV Virus
	Detection
	Jongmin Son, Wonyoung Choi, Seonghwan Shin, Jeonghyeon Do, and Jeong-Soo
	Lee
	Department of Electrical Engineering, POSTECH
	임피던스 바이오센싱 응용 분야를 위한 ECIS 기반의 Multi-well Array
TP1-320	Impedance Biosensor 제작 및 연구
TF 1-520	Seok Gyu Kim <sup>1</sup> , Da Hyun Kang <sup>1</sup> , Su Gwon Nam <sup>1</sup> , and Moon Gyu Jang <sup>1,2</sup> <sup>1</sup> School of Nano Convergence Technology, Hallym University, <sup>2</sup> Center of Nano
	Convergence Technology, Hallym University
	An Implantable UVC Sterilization Capsule Device for Biomedical
	Applications
TP1-321	Keodan Kim, Sangho Park, and Gunchul Shin
	School of Materials Science & Engineering, University of Ulsan
TP1-322	신개념 이온감응 소자 Gated lateral BJT의 Bio Transducer분야 응용 권혁춘
11 1 022	전력문   순천대학교
	Adhesive Hydrogel-integrated Soft Wearable Liquid Metal Composite
TD1 000	Electrode by Direct Laser Patterning
TP1-323	Jaehyon Kim <sup>1</sup> , Donghee Son <sup>1,2</sup>
	Demonstrate of Electrical and Ocean ten Englisher for the Unit of the Unit of the
	<sup>1</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University, <sup>2</sup> Department of Artificial Intelligence System Engineering, Sungkyunkwan University,
	<sup>2</sup> Department of Artificial Intelligence System Engineering, Sungkyunkwan University
	<sup>2</sup> Department of Artificial Intelligence System Engineering, Sungkyunkwan University Injectable and Conductive Hydrogels for Neural Interfacing and
TP1-324	<sup>2</sup> Department of Artificial Intelligence System Engineering, Sungkyunkwan University Injectable and Conductive Hydrogels for Neural Interfacing and Regeneration of Biological Tissues
TP1-324	<sup>2</sup> Department of Artificial Intelligence System Engineering, Sungkyunkwan University Injectable and Conductive Hydrogels for Neural Interfacing and
TP1-324	<sup>2</sup> Department of Artificial Intelligence System Engineering, Sungkyunkwan University Injectable and Conductive Hydrogels for Neural Interfacing and Regeneration of Biological Tissues Subin Jin, Heewon Choi, Donghee Son, and Mikyung Shin
TP1-324	<ul> <li><sup>2</sup>Department of Artificial Intelligence System Engineering, Sungkyunkwan University</li> <li>Injectable and Conductive Hydrogels for Neural Interfacing and Regeneration of Biological Tissues</li> <li>Subin Jin, Heewon Choi, Donghee Son, and Mikyung Shin</li> <li>Sungkyunkwan University</li> </ul>
TP1-324	<ul> <li><sup>2</sup>Department of Artificial Intelligence System Engineering, Sungkyunkwan University</li> <li>Injectable and Conductive Hydrogels for Neural Interfacing and Regeneration of Biological Tissues</li> <li>Subin Jin, Heewon Choi, Donghee Son, and Mikyung Shin</li> <li>Sungkyunkwan University</li> <li>Comparison of NIH/3T3 Cell Capacitance according to Impedance</li> <li>Pattern Size</li> <li>Da Hyun Kang<sup>1</sup>, Seok Gyu Kim<sup>1</sup>, Su Gwon Nam<sup>1</sup>, and Moon Gyu Jang<sup>1,2</sup></li> </ul>
	<ul> <li><sup>2</sup>Department of Artificial Intelligence System Engineering, Sungkyunkwan University</li> <li>Injectable and Conductive Hydrogels for Neural Interfacing and Regeneration of Biological Tissues</li> <li>Subin Jin, Heewon Choi, Donghee Son, and Mikyung Shin</li> <li>Sungkyunkwan University</li> <li>Comparison of NIH/3T3 Cell Capacitance according to Impedance</li> <li>Pattern Size</li> <li>Da Hyun Kang<sup>1</sup>, Seok Gyu Kim<sup>1</sup>, Su Gwon Nam<sup>1</sup>, and Moon Gyu Jang<sup>1,2</sup></li> <li>School of Nano Convergence Technology, Hallym University, <sup>2</sup>Center of Nano</li> </ul>
	<ul> <li><sup>2</sup>Department of Artificial Intelligence System Engineering, Sungkyunkwan University</li> <li>Injectable and Conductive Hydrogels for Neural Interfacing and Regeneration of Biological Tissues</li> <li>Subin Jin, Heewon Choi, Donghee Son, and Mikyung Shin</li> <li>Sungkyunkwan University</li> <li>Comparison of NIH/3T3 Cell Capacitance according to Impedance</li> <li>Pattern Size</li> <li>Da Hyun Kang<sup>1</sup>, Seok Gyu Kim<sup>1</sup>, Su Gwon Nam<sup>1</sup>, and Moon Gyu Jang<sup>1,2</sup></li> </ul>
	<ul> <li><sup>2</sup>Department of Artificial Intelligence System Engineering, Sungkyunkwan University</li> <li>Injectable and Conductive Hydrogels for Neural Interfacing and Regeneration of Biological Tissues</li> <li>Subin Jin, Heewon Choi, Donghee Son, and Mikyung Shin</li> <li>Sungkyunkwan University</li> <li>Comparison of NIH/3T3 Cell Capacitance according to Impedance</li> <li>Pattern Size</li> <li>Da Hyun Kang<sup>1</sup>, Seok Gyu Kim<sup>1</sup>, Su Gwon Nam<sup>1</sup>, and Moon Gyu Jang<sup>1,2</sup></li> <li>School of Nano Convergence Technology, Hallym University, <sup>2</sup>Center of Nano</li> </ul>
	<ul> <li><sup>2</sup>Department of Artificial Intelligence System Engineering, Sungkyunkwan University</li> <li>Injectable and Conductive Hydrogels for Neural Interfacing and Regeneration of Biological Tissues</li> <li>Subin Jin, Heewon Choi, Donghee Son, and Mikyung Shin</li> <li>Sungkyunkwan University</li> <li>Comparison of NIH/3T3 Cell Capacitance according to Impedance</li> <li>Pattern Size</li> <li>Da Hyun Kang<sup>1</sup>, Seok Gyu Kim<sup>1</sup>, Su Gwon Nam<sup>1</sup>, and Moon Gyu Jang<sup>1,2</sup></li> <li>School of Nano Convergence Technology, Hallym University, <sup>2</sup>Center of Nano Convergence Technology, Hallym University</li> </ul>
TP1-325	<ul> <li><sup>2</sup>Department of Artificial Intelligence System Engineering, Sungkyunkwan University</li> <li>Injectable and Conductive Hydrogels for Neural Interfacing and Regeneration of Biological Tissues</li> <li>Subin Jin, Heewon Choi, Donghee Son, and Mikyung Shin</li> <li>Sungkyunkwan University</li> <li>Comparison of NIH/3T3 Cell Capacitance according to Impedance</li> <li>Pattern Size</li> <li>Da Hyun Kang<sup>1</sup>, Seok Gyu Kim<sup>1</sup>, Su Gwon Nam<sup>1</sup>, and Moon Gyu Jang<sup>1,2</sup></li> <li>School of Nano Convergence Technology, Hallym University, <sup>2</sup>Center of Nano Convergence Technology, Hallym University</li> <li>A Highly Power-efficient LDO with Reliable Low Input Voltage Operation</li> </ul>



TP1-327	Self-healing Bioelectronic Artificial Vascular Graft with Antithrombotic Capability Soojung An, Heewon Choi, and Donghee Son Department of Electrical and Computer Engineering, Sungkyunkwan University
V. Quantum Te	echnology 분과
	ZONE 1 (1층 전시장)
TP1-328	Quantum Monte Carlo Simulation for Predicting Radiation Therapy Dose Hyeon Seong Jung, Ui Min Lee, Pamul Yadav, Jun Yong Lee, and Shi Ho Kim School of Integrated Technology, Yonsei University
TP1-329	Efficient Node Search in Binary Tree Using Quantum Walk Pamul Yadav, Junyong Lee, Uimin Lee, Hyeonseong Jung, and Shiho Kim School of Integrated Technology, Yonsei University
TP1-330	Implementation of Five-qubit Quantum Information Processing in Silicon Device: A Preliminary Investigation Junghee Ryu and Hoon Ryu KISTI
TP1-331	Constructing Ytterbium Ion Trap System for Quantum Computing Using Cryostat Junhee Cho, Myunghun Kim, Sehyeon Gwon, Keumhyun Kim, Hyegoo Lee, Sangsoo Han, and Moonjoo Lee Department of Electrical Engineering, POSTECH
학부생포스터	
	ZONE 4 (3층 로비)
TP1-332	A PVT-Compensated 14-Bit Time-to-Digital Converter for LiDAR Applications Yongjin Kwon, Yeseung Choi, and Shinwoong Kim Department of Electrical and Electronic Engineering, Handong Global University
TP1-333	Skin-adhesive Hydrocolloid Based OLED for Enhanced Light Therapeutics Yujin Kwak <sup>1</sup> , Seohyeon Kim <sup>1</sup> , Youngwoo Kim <sup>2</sup> , DongWoon Lee <sup>2</sup> , Yeji Shin <sup>1</sup> , Eou-Sik Cho <sup>2</sup> , Sang Jik Kwon <sup>2</sup> , HyoungSoon Youn <sup>3</sup> , JinHong Jeong <sup>3</sup> , and Yongmin Jeon <sup>1</sup> <sup>1</sup> Department of Biomedical Engineering, Gachon University, <sup>2</sup> Department of Electronic Engineering, Gachon University, <sup>3</sup> T&L Company

TP1-334	Thickness-dependent Electrical Properties of SnSe2 Field-Effect Transistors Using Reactive Ion Etching HanWoong Choi <sup>1</sup> , Jin-Hoo Seong <sup>1,2</sup> , Hyo-Chang Lee <sup>3</sup> , Sang-il Kim <sup>4</sup> , and TaeWan Kim <sup>1</sup> <sup>1</sup> Department of Electrical Engineering and Smart Grid Research Center, Jeonbuk National University, <sup>2</sup> Advanced Instrumentation Institute, KRISS, <sup>3</sup> Department of Semiconductor Science, Engineering and Technology, Korea Aerospace University, <sup>4</sup> Department of Materials Science and Engineering, University of Seoul
TP1-335	Adaptability of 4D Radar in Autonomous Driving: A PointNet-Based Point Cloud Data Analysis In Su Lee, Min Jun Kwon, Won Jun Choi, Ki Chan Kim, and Tae Ik Kang Department of Electronic Engineering, Myongji University
TP1-336	Double Gate MOSFET 에서의 HKMG 의 적용과 두께 조절을 통한 성능 최적 화 연구 최훈 <sup>1</sup> , 김대솔 <sup>1</sup> , 김도엽 <sup>1</sup> , 전영우 <sup>2</sup> , 김동현 <sup>2</sup> , 김진우 <sup>3</sup> <sup>1</sup> 중앙대학교 전자전기공학부, <sup>2</sup> 중앙대학교 화학신소재공학부, <sup>3</sup> 광운대학교 전자공학과
TP1-338	웨이퍼 레벨 3D 적층 메모리 제조의 수율 효율성에 관한 연구 정광휘, 권윤후, 김서영, 황찬우, 김사라은경 서울과학기술대학교 지능형반도체공학과
TP1-339	1200V급 β-Ga <sub>2</sub> O <sub>3</sub> Schottky Barrier Diode의 Edge Termination에 대한 연 구 이태은, 송창우, 박준영, 우솔아 부경대학교 전자공학과
TP1-340	Gate Controlled Thyristor 1T-DRAM의 Retention Time에 대한 연구 손지민, 우솔아 부경대학교 전자공학과
TP1-341	구리/옥사이드 하이브리드 본딩 전 다양한 플라즈마 영향 연구 임동현, 김민재, 권범성, 김혜교, 안종현, 김사라은경 서울과학기술대학교 지능형반도체공학과
TP1-342	2D PN (Te-MoS <sub>2</sub> ) Semiconductor-based High-performance Infrared Photodetector Shinhoi Kim <sup>1</sup> and Byungjin Cho <sup>1,2</sup>

	<sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University
TP1-343	Modulation of Lattice Structure and Electrical Properties of Graphene and MoS <sub>2</sub> through Surface Plasma Treatments Yoona Hwang <sup>1</sup> , Taehyeon Kim <sup>1</sup> , Seongho Kim <sup>1</sup> , Danbi Lee <sup>1</sup> , Yasir Hassan <sup>1</sup> , Minji Kang <sup>2</sup> , Hyeong-U Kim <sup>2</sup> , and Min Sup Choi <sup>1</sup> <sup>1</sup> Chungnam National University, <sup>2</sup> KIMM
TP1-344	Comparison of Electrical Characteristics of MoS Transistors with Different h-BN Stacking and Contact Methods Sungbin Lee, Wonseop Lee, Taehwan Lee, Minju Kim, and Min Sup Choi Department of Materials Science and Engineering, Chungnam National University
TP1-345	Effect of Oxidation on Doping Concentration of ZnSnN <sub>2</sub> Grown by Reactive RF Magnetron Sputtering Dohyun Kim <sup>1</sup> , Juchan Hwang <sup>1</sup> , and Kwangwook Park <sup>1,2</sup> <sup>1</sup> Division of Advanced Materials Engineering, Jeonbuk National University, <sup>2</sup> Hydrogen and Fuel Cell Research Center, Jeonbuk National University
TP1-346	Ferroelectric-metalField-effectTransistor의MetalWorkFunctionVariation 특성에 대한 연구하병주 <sup>1</sup> , 김동영 <sup>2</sup> , 윤택한 <sup>2</sup> , 우솔아 <sup>2</sup> <sup>1</sup> 부경대학교 물리학과, <sup>2</sup> 부경대학교 전자공학과
TP1-347	Ferroelectric-metal Field-effect Transistor의 Memory Window 특성에 대 한 연구 김동영 <sup>1</sup> , 하병주 <sup>2</sup> , 윤택한 <sup>1</sup> , 우솔아 <sup>1</sup> <sup>1</sup> 부경대학교 전자공학과, <sup>2</sup> 부경대학교 물리학과
TP1-348	Oxidized MoS <sub>2</sub> -based Synapse with Robust and Low Power Operation Changwoo Pyo, Hyunsoo Kim, Juyeong Jung, and Myungsoo Kim UNIST
TP1-349	Interplay between Optoelectronic and Structural Changes during Thermal Annealing of 3D Multi-cation Metal Halide Perovskite Thin Films Taehyun Kong <sup>1</sup> , Yongjin Kim <sup>1</sup> , Heebeom Ahn <sup>1</sup> , Hyeonmin Choi <sup>1</sup> , Eunje Park <sup>1</sup> , Youhyun Nam <sup>1</sup> , Takhee Lee <sup>2</sup> , and Keehoon Kang <sup>1</sup> <sup>1</sup> Department of Materials Science and Engineering, Seoul National University, <sup>2</sup> Department of Physics and Astronomy, Seoul National University

Xe-LPP 방식에서의 EUV 관련 생성 효율의 최적화 연구를 위한 다종물리(열- 기계-광학 연계) 해석           TP1-350         오세형 <sup>1</sup> , 전호성 <sup>1</sup> , 오전형 <sup>1</sup> , 오이ŋ Gun Lee <sup>3</sup> , Haekweon Jung <sup>3</sup> , 이온호 <sup>1,2</sup> <sup>1</sup> Department of Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> Department of Smart Fab. Technology, Sungkyunkwan University, <sup>3</sup> PhD Center, Esol Inc.           TP1-351         High Responsive InSe Based Photodetector Using RF Magnetron Sputtering           Yedam Kim <sup>1</sup> , Minyoung Cho <sup>1</sup> , and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University           Reduction of Contact Resistance in Tellurium Field-Effect Transistor Achieved by Graphene Interlayer Yeongeun Kwon <sup>1</sup> and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University           TP1-352           TP1-353           TP1-354           Reduction of Contact Resistance in Tellurium Field-Effect Transistor Achieved by Graphene Interlayer Yeongeun Kwon <sup>1</sup> and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University           Dielectric Properties of MIS Capacitors Utilizing the Nb <sub>2</sub> O <sub>5</sub> Oxidized from 2D NbS <sub>2</sub> TP1-353           TP1-354           Enhancing Schottky Diodes Performance with MSM-structured Organic Semiconductors for High-performance Electronics Bum Hwan Kim, Ji Hyeok Hwang, Jae Eun Kim, Da Unagu, Jin Seok Yoon, Nak Hee Kang, Sam Nyung Yi, Hyung Soo Ahn, Kyoung Hwa Kim, and Young Tea Chun Division of Electronics and Electrical Information Engineering, Korea Mariti		
TP1-350 오세형 <sup>1</sup> , 연호철 <sup>1</sup> , 오성철 <sup>1</sup> , Dong Gun Les <sup>8</sup> , Haekweon Jung <sup>8</sup> , 이문호 <sup>1,2</sup> <sup>1</sup> Department of Mechanical Engineering. Sungkyunkwan University. <sup>2</sup> Department of Smart Fab. Technology, Sungkyunkwan University, <sup>3</sup> RnD Center, Esol Inc. High Responsive InSe Based Photodetector Using RF Magnetron Sputtering Yedam Kim <sup>1</sup> , Minyoung Choi <sup>1</sup> , and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Advanced Material Engineering, Chungbuk National University Reduction of Contact Resistance in Tellurium Field-Effect Transistor Achieved by Graphene Interlayer Yeongeun Kwon <sup>1</sup> and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University TP1-352 TP1-353 TP1-353 TP1-353 TP1-354 Enhancing Schottky Diodes Performance With MSM-structured Organic Semiconductors for High-performance Electronics Bum Hwan Kim, Ji Hyeok Hwang, Jae Eun Kim, Da Un Jeong, Jin Seok Yoon, Nak Hee Kang, Sam Nyung Yi, Hyung Soo Ahn, Kyoung Hwa Kim, and Young Tea Chun Division of Electronics and Electrical Information Engineering, Korea Maritime and Ocean University TP1-355 Solution-processed MoS Based Robust RRAM with Low Power Switching and High Uniformity for Large-scale Fabrication Seungchan Lee, Changwoo Pyo, Dahyeon Kim, Seunghyeon Seo, and Myungsoo Kim UNIST	TP1-350	Xe-LPP 방식에서의 EUV 광원 생성 효율의 최적화 연구를 위한 다중물리(열-
TP1-351 이 전도 1 전		
Smart Fab. Technology, Sungkyunkwan University, <sup>3</sup> RnD Center, Esol Inc.           High Responsive InSe Based Photodetector Using RF Magnetron Sputtering           Yedam Kim <sup>1</sup> , Minyoung Choi <sup>1</sup> , and Byunglin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Contact Resistance in Tellurium Field-Effect Transistor Achieved by Graphene Interlayer Yeongeun Kwon <sup>1</sup> and Byunglin Cho <sup>1,2</sup> TP1-352         Reduction of Contact Resistance in Tellurium Field-Effect Transistor Achieved by Graphene Interlayer Yeongeun Kwon <sup>1</sup> and Byunglin Cho <sup>1,2</sup> TDepartment of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University           TP1-353         Dielectric Properties of MIS Capacitors Utilizing the Nb <sub>2</sub> O <sub>5</sub> Oxidized from 2D Nb <sub>2</sub> Minhee Kim <sup>1</sup> and Byunglin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University           TP1-354         Enhancing Schottky Diodes Performance With MSM-structured Organic Semiconductors for High-performance Electronics           Bum Hwan Kim, Ji Hyeek Hwang, Jae Eun Kim, Da Un Jeong, Jin Seek Yoon, Nak Hee Kang, Sem Nyung Yi, Hyung Soo Ahn, Kyoung Hwa Kim, and Young Tee Chun Division of Electronics and Electrical Information Engineering, Koree Maritime and Ocean University           TP1-355         Solution-processed MoS Based Robust RRAM with Low Power Switching and High Uniform		
TP1-351         High Responsive InSe Based Photodetector Using RF Magnetron Sputtering Yedam Kim <sup>1</sup> , Minyoung Choi <sup>1</sup> , and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University           TP1-352         Reduction of Contact Resistance in Tellurium Field-Effect Transistor Achieved by Graphene Interlayer Yeongeun Kwon <sup>1</sup> and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University           TP1-353         Dielectric Properties of MIS Capacitors Utilizing the Nb <sub>2</sub> O <sub>5</sub> Oxidized from 2D NbS <sub>2</sub> Minhee Kim <sup>1</sup> and Byungjin Cho <sup>1,2</sup> Dipartment of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University           TP1-354         Enhancing Schottky Diodes Performance with MSM-structured Organic Semiconductors for High-performance Electronics Bum Hwan Kim, Ji Hyeok Hwang, Jae Eun Kim, Da Un Jeong, Jin Seok Yoon, Nak Hee Kang, Sam Nyung Yi, Hyung Soo Ahn, Kyoung Hwa Kim, and Young Tea Chun Division of Electronics and Electrical Information Engineering, Korea Maritime and Ocean University           TP1-355         Solution-processed MoS Based Robust RRAM with Low Power Switching and High Uniformity for Large-scale Fabrication Seungchan Lee, Changwoo Pyo, Dahyeon Kim, Seunghyeon Seo, and Myungsoo Kim UNIST           TP1-356         Sixli ERJIMI INE Cul JII INE Ly IN		
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TP1-353         Dielectric Properties of MIS Capacitors Utilizing the Nb <sub>2</sub> O <sub>5</sub> Oxidized from 2D NbS <sub>2</sub> Minhee Kim <sup>1</sup> and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University           TP1-354         Enhancing Schottky Diodes Performance with MSM-structured Organic Semiconductors for High-performance Electronics           Bum Hwan Kim, Ji Hyeok Hwang, Jae Eun Kim, Da Un Jeong, Jin Seok Yoon, Nak Hee Kang, Sam Nyung Yi, Hyung Soo Ahn, Kyoung Hwa Kim, and Young Tea Chun Division of Electronics and Electrical Information Engineering, Korea Maritime and Ocean University           TP1-355         Solution-processed MoS Based Robust RRAM with Low Power Switching and High Uniformity for Large-scale Fabrication Seungchan Lee, Changwoo Pyo, Dahyeon Kim, Seunghyeon Seo, and Myungsoo Kim UNIST           TP1-356         열처리 분위기에 따른 Cul 기반 반도체 박막의 특성 연구 정혜린, 전희실, 흥기현		<sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National
TP1-353       2D NbS2         Minhee Kim <sup>1</sup> and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University         TP1-354       Enhancing Schottky Diodes Performance with MSM-structured Organic Semiconductors for High-performance Electronics         Bum Hwan Kim, Ji Hyeok Hwang, Jae Eun Kim, Da Un Jeong, Jin Seok Yoon, Nak Hee Kang, Sam Nyung Yi, Hyung Soo Ahn, Kyoung Hwa Kim, and Young Tea Chun Division of Electronics and Electrical Information Engineering, Korea Maritime and Ocean University         TP1-355       Solution-processed MoS Based Robust RRAM with Low Power Switching and High Uniformity for Large-scale Fabrication Seungchan Lee, Changwoo Pyo, Dahyeon Kim, Seunghyeon Seo, and Myungsoo Kim UNIST         TP1-356		University
TP1-353Minhee Kim1 and Byungjin Cho1.2 1 Department of Advanced Material Engineering, Chungbuk National University, 2 Department of Urban, Energy, and Environmental Engineering, Chungbuk National UniversityTP1-354Enhancing Schottky Diodes Performance with MSM-structured Organic Semiconductors for High-performance Electronics Bum Hwan Kim, Ji Hyeok Hwang, Jae Eun Kim, Da Un Jeong, Jin Seok Yoon, Nak Hee Kang, Sam Nyung Yi, Hyung Soo Ahn, Kyoung Hwa Kim, and Young Tea Chun Division of Electronics and Electrical Information Engineering, Korea Maritime and Ocean UniversityTP1-355Solution-processed MoS Switching and High Uniformity for Large-scale Fabrication Seungchan Lee, Changwoo Pyo, Dahyeon Kim, Seunghyeon Seo, and Myungsoo Kim UNISTTP1-356열처리 분위기에 따른 Cul 기반 반도체 박막의 특성 연구 정혜린, 전희실, 홈기현		Dielectric Properties of MIS Capacitors Utilizing the Nb <sub>2</sub> O <sub>5</sub> Oxidized from
IP1-353 <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National UniversityTP1-354Enhancing Schottky Diodes Performance with MSM-structured Organic Semiconductors for High-performance Electronics Bum Hwan Kim, Ji Hyeok Hwang, Jae Eun Kim, Da Un Jeong, Jin Seok Yoon, Nak Hee Kang, Sam Nyung Yi, Hyung Soo Ahn, Kyoung Hwa Kim, and Young Tea Chun Division of Electronics and Electrical Information Engineering, Korea Maritime and Ocean UniversityTP1-355Solution-processed MoS Based Robust RRAM with Low Power Switching and High Uniformity for Large-scale Fabrication Seungchan Lee, Changwoo Pyo, Dahyeon Kim, Seunghyeon Seo, and Myungsoo Kim UNISTTP1-356曾처리 분위기에 따른 Cul 기반 반도체 박막의 특성 연구 정혜린, 전희설, 흥기현		2D NbS <sub>2</sub>
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TP1-354Enhancing Schottky Diodes Performance with MSM-structured Organic Semiconductors for High-performance Electronics Bum Hwan Kim, Ji Hyeok Hwang, Jae Eun Kim, Da Un Jeong, Jin Seok Yoon, Nak Hee Kang, Sam Nyung Yi, Hyung Soo Ahn, Kyoung Hwa Kim, and Young Tea Chun Division of Electronics and Electrical Information Engineering, Korea Maritime and Ocean UniversityTP1-355Solution-processed MoS Suitching and High Uniformity for Large-scale Fabrication Seungchan Lee, Changwoo Pyo, Dahyeon Kim, Seunghyeon Seo, and Myungsoo Kim UNISTTP1-356열처리 분위기에 따른 Cul 기반 반도체 박막의 특성 연구 정혜린, 전희설, 홍기현		<sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National
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TP1-404	Improvement of BEOL Compatible Indium-based-oxide TFT for DRAM Dahui Jeon, InHong Hwang, and In-Hwan Baek Department of Chemical Engineering, Inha University
TP1-405	Electrical and Optical Properties of 2D TMD Heterojunction Structures Jae Hyeop Lee <sup>1</sup> , Dong Hwi Choi <sup>1</sup> , Guen Hyung Oh <sup>2</sup> , Tae Wan Kim <sup>2</sup> , and Jae Cheol Shin <sup>1</sup> <sup>1</sup> Dongguk University, <sup>2</sup> Jeonbuk National University
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TP1-410	반도체 테스트 장비의 DPS 데이터 전송 효율 개선을 위한 FPGA 기반 SPI 모듈 설계 Jonghee Park <sup>1</sup> , Hwarang Baek <sup>1</sup> , Jiseok Lee <sup>1</sup> , Junhyeong Ji <sup>1</sup> , and Youbean Kim <sup>2</sup> <sup>1</sup> Department of Electronic Engineering, Myongji University, <sup>2</sup> Department of Semiconductor Engineering, Myongji University

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	Jinho Jang <sup>1</sup> , Minji Kang <sup>1</sup> , Injoo Kim <sup>2</sup> , and Sungdong Kim <sup>1</sup>
	<sup>1</sup> Department of Mechanical System Design Engineering, Seoul National University
	of Science and Technology, <sup>2</sup> Department of Mechanical Design and Robot
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	Wookyung Lee <sup>1</sup> , Siye Lee <sup>1</sup> , Injoo Kim <sup>2</sup> , and Sungdong Kim <sup>1</sup>
TP1-458	<sup>1</sup> Department of Mechanical System Design Engineering, Seoul National University
	of Science and Technology, <sup>2</sup> Department of Mechanical Design and Robot
	Engineering, Seoul National University of Science and Technology
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TP1-488	A Simulation of Electrical Properties in the Induced Systems Se Hun Kim <sup>1</sup> , Jik Hyeon Ham <sup>1</sup> , and Seock-Kyun Son <sup>1,2</sup> <sup>1</sup> Department of Physics, Kyung Hee University, <sup>2</sup> Department of Information Display, Kyung Hee University

TP1-489	VWW 특화 RISC-V 프로세서 기반 CPU-NPU 하이브리드 프로세서 설계 Jaeseok Lee, Jeonghwan Ahn, Gisan Ji, and Sungju Ryu Department of Electronic Engineering, Sogang University
TP1-490	Improving the Current Density of IGZO TFT by Corrugated Substrate Ye Won Jeong <sup>1</sup> , Jeong Ha Yoon <sup>1</sup> , Taewon Seo <sup>1</sup> , and Yoonyoung Chung <sup>1, 2, 3</sup> <sup>1</sup> Department of Electrical Engineering, POSTECH, <sup>2</sup> Department of Semiconductor Engineering, POSTECH, <sup>3</sup> Center for Semiconductor Technology Convergence, POSTECH
TP1-491	Highly-stable a-IGZO TFT under PBS Condition by Passivation with Hydrogen Plasma Treatment Jeongha Yoon <sup>1</sup> , Yewon Jeong <sup>1</sup> , Taewon Seo <sup>1</sup> , and Yoonyoung Chung <sup>1,2,3</sup> <sup>1</sup> Department of Electrical Engineering, POSTECH, <sup>2</sup> Department of Semiconductor Engineering, POSTECH, <sup>3</sup> Center for Semiconductor Technology Convergence, POSTECH
TP1-492	BaZrO <sub>3</sub> /MgO Templated Epitaxy Enables Three Orders of Magnitude Conductivity Increase in Ba <sub>0.95</sub> La <sub>0.05</sub> SnO <sub>3</sub> Films on Al <sub>2</sub> O <sub>3</sub> Substrates, Promoting Very High Transparency and X-band Electromagnetic Shielding Youngkyoung Ha <sup>1</sup> , Jingyeong Jeon <sup>1</sup> , Subhin Hwang <sup>1</sup> , Judith L. MacManus- Driscoll <sup>2</sup> , and Shinbuhm Lee <sup>1</sup> <sup>1</sup> DGIST, <sup>2</sup> University of Cambridge
TP1-493	Random Resistance of Graphene according to Self-Assembled Monolayers and Application of Physically Unclonable Functions Eun Bee Ko <sup>2</sup> , Su Bin Lee <sup>1</sup> , Si Heon Lim <sup>2</sup> , Min Seo Kim <sup>1</sup> , Byung Cheol Jang <sup>3</sup> , Ho Cheon Yoo <sup>1</sup> , and Hyun Ho Kim <sup>2</sup> <sup>1</sup> Department of Electronic Engineering, Gachon University, <sup>2</sup> Department of Energy Engineering Convergence, Kumoh National Institute of Technology, <sup>3</sup> School of Electronics and Electrical Engineering, Kyungpook University
TP1-494	하프늄 기반 산화물을 활용한 실리콘 나노선 메모리 소자에 대한 특성 연구 박종문, 임두혁 경기대학교

TP1-495	Stacked Structure Infrared Photodetector Utilizing Colloidal Quantum Dots Ji Hyeon Woo and Seong-Yong Cho Department of Photonics and Nanoelectronics, Hanyang University ERICA
TP1-496	메모리 효율성 향상을 위한 DNN 경량화 기술연구 Hoyong Jeong, Jaeseok Moon, Jinsung Lee, Jaeseong Byun, Sehyun Hwang, Dongseok Oh, Jincheol Yang, and Sukju Kang Department of Electrical Engineering, Sogang University
TP1-497	Understanding Process Instability Triggered by Built-in Dipole Moments in Janus MoSSe Seon Yeon Choi <sup>1</sup> , Sun Woo Kim <sup>1,2</sup> , Si Heon Lim <sup>1,2</sup> , Eun Bee Ko <sup>1</sup> , Seunghyun Kim <sup>3</sup> , Yun Chang Park <sup>4</sup> , Sunghun Lee <sup>5</sup> , and Hyun Ho Kim <sup>1,2</sup> <sup>1</sup> School of Materials Science and Engineering, Kumoh National Institute of Technology, <sup>2</sup> Department of Energy Engineering Convergence, Kumoh National Institute of Technology, <sup>3</sup> Department of Chemical Engineering, POSTECH, <sup>4</sup> Department of Measurement and Analysis, National Nanofab Center, <sup>5</sup> Division of Nanotechnology, Convergence Research Institute, DGIST
TP1-498	Analysis of Hot Carrier Injection (HCI) and Fowler-Norheim (FN) Tunneling Mechanisms in Charge Trap Flash (CTF) Memory Device Youn Seok Kye, Jae Yeon Park, and Sangwan Kim Department of Electronic Engineering, Sogang University
TP1-499	DRAM Write Recovery Speed 연구 Ji Won Son, Jeon Woong Kang, Seo Yoon Lee, and Sung-Woong Chung POSTECH
TP1-500	AnalysisonElectricalPerformanceofNanosheetFETwithAsymmetric Inner Spacer ThicknessWon Gi Hong and Hyunwoo KimDepartment of Electrical and Electronics Engineering, Konkuk University
TP1-501	Solution-Processed Metal-Oxide Thin-Film Transistors Fabricated at Low Temperatures by Metal Ion Doping Eun-Ha Kim, Chae-Eun Kim, Ho-Jun Cha, Yeon-Eui Lee, Su-Been Kim, Se-Ryong Park, and Tae-Jun Ha Department of Electronic Materials Engineering, Kwangwoon University



	An Overall Study of Raman Spectroscopy for Two-dimensional
	Materials
TP1-502	Mubin Park <sup>1</sup> , Jyyoun Han <sup>1</sup> , and Seok-Kyun Son <sup>1,2</sup>
	<sup>1</sup> Department of Physics, Kyung Hee University, <sup>2</sup> Department of Information Display,
	Kyung Hee University
	Voltage Dependence of Kink Effect in Floating Body PD-SOI MOSFETs
TP1-503	Wongi Cho and Seonghearn Lee
	Department of Electronics Engineering, Hankuk University of Foreign Studies
	Incandescent of Graphene and High Electrical Characteristics on Ge
	Wafer by CVD Method
TP1-504	Gyu-Seock Ko <sup>1</sup> , Do-Hoon Kim <sup>1</sup> , Hyeon-Sik Jang <sup>2</sup> , and Seok-Kyun Son <sup>1,3</sup>
	<sup>1</sup> Department of Physics, Kyung Hee University, <sup>2</sup> School of Semiconductor Science
	& Technology, Jeonbuk National University, <sup>3</sup> Department of Information Display,
	Kyung Hee University
	Transfer Methods of Monolayer Graphene
TP1-505	Minjun Kang, Jiyong Park, and Yong-Sun Kim
	Ajou University
	High-Performance Resistive Random Access Memory based on
TP1-506	Solution-Processed High-k Dielectrics
	Chae-Eun Kim, Eun-Ha Kim, Da-Bin Seo, Se-Ryong Park, and Tae-Jun Ha
	Department of Electronic Materials Engineering, Kwangwoon University
	Analyzing of Self-heating Effect of a-ITZO Thin Film Transistor by
	Using Thremoreflectance Microscopy for Better Heat Dissipation in
	Channel Thickness
TP1-507	Yongjin Shin, Taewon Jin, Sanghoon Shin and Younghyun Kim
	Department of Photonics and Nanoelectronics, BK21 FOUR ERICA-ACE Center,
	Hanyang University
	Wearable ECG and GSR Acquisition System with Motion Artifacts
TP1-508	Robustness
	Seokhan Jeong, Jiho Kim, Minho Sung, Jeongmin Cha, Taeryoung Seol, and
	Junghyup Lee
	DGIST

TP1-509	Enhancing Nonlinearity of LTP/LTD in HfO <sub>2</sub> –Based Synaptic Devices for Spiking Neural Networks Jong Min Baek <sup>1</sup> , Jung Hyeon Gong <sup>1</sup> , Chae Min Yeom <sup>1</sup> , Hyeon Seung Lee <sup>1</sup> , Hyuk Min Kwon <sup>2</sup> , and Hi Deok Lee <sup>1</sup> <sup>1</sup> Chungnam National University, <sup>2</sup> Semiconductor Convergence Campus, Korea Polytechnics College
TP1-510	Attention in Attention-Based One-Encoder-Two-Decoder Network for Image Deblurring Ji-Soo Sin and Ho Sub Lee Kumoh National Institute of Technology
TP1-511	Multi-Kernel Strip Pooling-Based Attention Network for Super Resolution Jong Youn Lee, Gwang Nam An, Do Hyeon Seo, Chan Mee Kim, and Ho Sub Lee Kumoh National Institute of Technology
TP1-512	Study on the Methods to Improve Switching Variability and Reliability in Self-rectifying Resistive Switching Memory Yura Oh, Sua Han, and Hae Jin Kim Department of Materials Science and Engineering, Myongji University
TP1-513	CNN-LSTM 모델 기반 반도체 제조 공정 이상 탐지 방안 Sejin Park <sup>1</sup> , Hye-Jung Yoon <sup>2</sup> <sup>1</sup> University of Seoul, <sup>2</sup> Seoul National University
TP1-514	Optimizing MoS <sub>2</sub> Properties through Substrate-Heated Sputter Deposition: Exploring Crystallinity and Deposition Characteristics Ha Yeon Choi <sup>1</sup> , Tae Gyu Ryu <sup>1</sup> , Hye Seong Park <sup>1</sup> , Hyuk Min Kwon <sup>2</sup> , and Hi Deok Lee <sup>1</sup> <sup>1</sup> Chungnam National University, <sup>2</sup> Semiconductor Convergence Campus of Korea Polytechnics College
TP1-515	2차 고조파 측정법을 이용한 강자성체 소자의 스핀 토크 측정 피진주, 김종도, 김하늘, 임은지, 김상훈 울산대학교 물리학과
TP1-516	Hash Table을 활용한 Adaptive Learning-Based FTL Myung hoon Hyun Sungkyunkwan University

	동적 비전 센서의 Verilog 디지털회로설계 및 시뮬레이션
TP1-517	김성주
	성균관대학교 반도체시스템공학과
	Improving the Reliability Characteristics Using Doping Layer between
	WLs in 3D NAND Flash Memory
TD1 E10	Hyewon Kyung <sup>1,2</sup> , Jungil Bae <sup>1,2</sup> , Donghoon Lee <sup>1,2</sup> , Kijun Lim <sup>1,2</sup> , Yunejae Suh <sup>1,3</sup> ,
TP1-518	Sanghyuk Lee <sup>1,3</sup> , and Daewoong Kang <sup>1</sup>
	<sup>1</sup> Next Generation Semiconductor Convergence and Open Sharing System, <sup>2</sup> Chung-
	Ang University, <sup>3</sup> Soongsil University
	Analysis of Cell Characteristics Depending on Vertical Channel
	Structure in 3D NAND Flash
	Donghoon Lee <sup>1,2</sup> , Hyewon Kyung <sup>1,2</sup> , Jungil Bae <sup>1,2</sup> , Yunjae Seo <sup>1,3</sup> , Sanghyuk Lee
TP1-519	<sup>1,4</sup> , Kijun Lim <sup>1,2</sup> , and Daewoong Kang <sup>1</sup>
	<sup>1</sup> Next Generation Semiconductor Convergence and Open Sharing System, Seoul
	National University, <sup>2</sup> School of Electrical and Electronics Engineering, Chung-ang
	University, <sup>3</sup> Department of Electronic Engineering, Soongsil University, <sup>4</sup> Department
	of Materials Science and Engineering, Soongsil University
	A New Concept to Improve the Retention Characteristics in 3D NAND
	Flash
	Yunejae Suh <sup>1,2</sup> , Sanghyuk Lee <sup>1,3</sup> , Hyewon Kyung <sup>1,4</sup> , Jungil Bae <sup>1,4</sup> , Donghoon
TP1-520	Lee <sup>1,4</sup> , Kijun Lim <sup>1,4</sup> , and Daewoong Kang <sup>1</sup>
	<sup>1</sup> Next Generation Semiconductor Convergence and Open Sharing System,
	<sup>2</sup> Department of Electronic Engineering, Soongsil University, <sup>3</sup> Department of
	Materials Science and Engineering, Soongsil University, <sup>4</sup> School of Electrical and
	Electronics Engineering, Chung-ang University
	New Process to Fabricate the CT(Charge Trap)-Cut in 3D NAND Flash
	to Improve Reliability
	Kijun Lim <sup>1,2</sup> , Hyewon Kyung <sup>1,2</sup> , Jungil Bae <sup>1,2</sup> , Yunjae Suh <sup>1,3</sup> , Donghoon Lee <sup>1,2</sup> ,
TP1-521	Sanghyuk Lee <sup>1,3</sup> , and Daewoong Kang <sup>1</sup>
	<sup>1</sup> Next Generation Semiconductor Convergence and Open Sharing System, <sup>2</sup> School
	of Electrical and Electronics Engineering, Chung-ang University, <sup>3</sup> Department of
TP1-522	Electronic Engineering, Soongsil University, <sup>4</sup> Department of Materials Science and
	Engineering, Soongsil University
	Analysis of Trap Effect in Back Oxide to Control the Cell Current in 3D
	NAND Flash
	Sanghyuk Lee <sup>1,2</sup> , Yunejae Suh <sup>1,3</sup> , Hyewon Kyung <sup>1,4</sup> , Jungil Bae <sup>1,4</sup> , Donghoon Lee <sup>1,4</sup> , Kijun Lim <sup>1,4</sup> , and Daewoong Kang <sup>1</sup>
	<sup>1</sup> Next Generation Semiconductor Convergence and Open Sharing System,

	<sup>2</sup> Department of Materials Science and Engineering, Soongsil University, <sup>3</sup> Department of Electronic Engineering, Soongsil University, <sup>4</sup> School of Electrical and Electronics Engineering, Chung-ang University
	A New Approach to Improve Cell Characteristics of 3D NAND Flash
TP1-523	Using Indium-gallium-zinc-oxide Channels.
	Jungil Bae <sup>1,2</sup> , Hyewon Kyung <sup>1,2</sup> , Donghun Lee <sup>1,2</sup> , Kijun Lim <sup>1,2</sup> , Yunejae Suh <sup>1,3</sup> ,
	Sanghyuk Lee <sup>1,4</sup> , and Daewoong Kang <sup>1</sup>
	<sup>1</sup> Next Generation Semiconductor Convergence and Open Sharing System,
	<sup>2</sup> Department of Electrical and Electronics Engineering, Chung-Ang University,
	<sup>3</sup> Department of Electronic Engineering, Soongsil University, <sup>4</sup> Department of
	Materials Science and Engineering, Soongsil University

#### 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

[FP1] 포스터세션 2024년 1월 26일(금) 09:00-17:25 저자 Q&A 세션: 10:45-11:25

A. Interconnect & Package 분과	
	ZONE 4 (3층 로비)
FP1-001	Optimization of O <sub>2</sub> Plasma Treatment on Cu Surface for Hybrid Cu Bonding Sangwoo Park <sup>1</sup> , Sangmin Lee <sup>1</sup> , Junyoung Choi <sup>2</sup> , and Sarah Eunkyung Kim <sup>1</sup> <sup>1</sup> Department of Semiconductor Engineering, Seoul National University of Science and Technology, <sup>2</sup> Department of Electrical and Information Engineering, Seoul National University of Science and Technology
FP1-002	Potential Use of Fly Cutting Method for Cu/Polymer Planarization in Hybrid Bonding Sangmin Lee <sup>1</sup> , Suin Jang <sup>2</sup> , Sangwoo Park <sup>1</sup> , and Sarah Eunkyung Kim <sup>1</sup> <sup>1</sup> Department of Semiconductor Engineering, Seoul National University of Science and Technology, <sup>2</sup> Research Center for Advanced Semiconductor Packaging, Seoul National University of Science and Technology
FP1-003	Evaluation of PVD SiCN for Cu/SiCN Hybrid Bonding Junyoung Choi <sup>1</sup> , Sangwoo Park <sup>2</sup> , Sangmin Lee <sup>2</sup> , and Sarah Eunkyung Kim <sup>2</sup> <sup>1</sup> Department of Electrical and Information Engineering, Seoul National University of Science and Technology, <sup>2</sup> Department of Semiconductor Engineering, Seoul National University of Science and Technology
FP1-004	A Study of Surface Treatment on SiO2/SiO2 Bonding for Cu/SiO2 Hybrid Wafer Bonding Joong-Heon Kim <sup>1</sup> , Sung-Min Park <sup>1</sup> , Sang Hyun Jung <sup>1</sup> , and Kyung-Ho Park <sup>2</sup> <sup>1</sup> System IC Platform Lab, <sup>2</sup> Advanced Packaging TF, KANC
FP1-005	Reliability Investigations of Polymer-Based Redistribution Layers (RDL) by Oxygen and Moisture Ji-Youn Kwak <sup>1</sup> , Emmanuel Chery <sup>2</sup> , Julien Bertheau <sup>2</sup> , John Slabbekoorn <sup>2</sup> , Joke De Messemaeker <sup>2</sup> , Eric Beyne <sup>2</sup> , and Ju-Young Kim <sup>1</sup> <sup>1</sup> UNIST, <sup>2</sup> imec



FP1-006	ALD ZnO 확산방지층이 Cu와 Ru 배선의 계면접착에너지에 미치는 영향 정대윤 <sup>1,2</sup> , 김가희 <sup>1,2</sup> , 김민진 <sup>1,2</sup> , 손예슬 <sup>3</sup> , Yuki Mori <sup>3,4</sup> , 김수현 <sup>3</sup> , <sup>5</sup> , 박영배 <sup>1,2</sup> <sup>1</sup> 안동대학교 신소재공학부, <sup>2</sup> 안동대학교 청정에너지 소재기술연구센터, <sup>3</sup> 울산과학기술원 반 도체 소재부품 대학원, <sup>4</sup> Chemical Materials Development Department, TANAKA Precious Metals, <sup>5</sup> 울산과학기술원 신소재공학과
FP1-007	Low-temperature Hybrid Bonding for Enhanced Semiconductor Integration and Reliability Youngju Sim, Gyeong-Seok Hwang, and Ju-Young Kim UNIST
FP1-008	The Study of the Erosion and Dishing Shape in the Cu CMP Process for 3D Hybrid Bonding Sang-Soo Kim, Su-Jeong Kang, Won-Youl Shin, Ju-Young An, Min-Jae Kim, Sungmin Park, Dongkeun Lee, and Kyung-Ho Park Advanced Packaging TF, KANC
FP1-009	저온 구리 접합 성능 향상을 위한 금속 패시베이션 결정성에 관한 연구 Min Seong Jeong, Sang Woo Park, Yeon Ju Kim, Ji Hoon Kim, and Jong Kyung Park Seoul National University of Science and Technology
FP1-010	대기압 플라즈마 표면 처리 활성화를 이용한 웨이퍼 본딩 기술 Wonyoung Choi, Bumki Moon, Kyeongbin Lim, Yongjoo Lee, Yongin Lee, Seung ho Han, Nungpyo Hong, and Minwoo Rhee Mechatronics Research, Samsung Electronics Co., Ltd.
FP1-011	Low Temperature Cu/Polymer Hybrid Bonding for 3D Multi-chip Stacking Process Ji-Hun-Kim, Yeon-Ju Kim, Min-Seong Jung, Sang-Woo Park, and Jong Kyung Park Department of Semiconductor Engineering, Seoul National University of Science and Technology
FP1-012	AI 및 수치해석 시뮬레이션을 활용한 반도체 패키지 열 기계적 유효 물성 모델 링 방법 설계 Jeong-Hyeon Park <sup>1</sup> , Sukwon Jang <sup>2</sup> , Sunggu Kang <sup>2</sup> , Sungho Mun <sup>2</sup> , Jaechoon Kim <sup>2</sup> , and Eun-Ho Lee <sup>1</sup> <sup>1</sup> Sungkyunkwan University, <sup>2</sup> Samsung Electronics Co., Ltd.
FP1-013	Reflow Temp Profile 제어를 통한 Sn Micro-bump Ball Shape 개선 연구 Beomwoo Lee SK hynix

	Analysis of Fermi Level Pinning of Metal-InGaZnO Junction with
FP1-014	Analysis of Fermi Level Pinning of Metal-InGazno Sunction with Interfacial Self-assembled Monolayer Sungbin Lim <sup>1</sup> , Dong-Gyun Mah <sup>2</sup> , Won-Ju Cho <sup>2</sup> , and Hamin Park <sup>1</sup> <sup>1</sup> Department of Electronic Engineering, Kwangwoon University, <sup>2</sup> Department of Electronic Materials Engineering, Kwangwoon University
FP1-015	A Study of Signal Integrity in Hybrid Bonding with Void Chan-Woong Park <sup>1,2</sup> and Kee-Won Kwon <sup>1,2</sup> <sup>1</sup> Department of Electrical and Computer Engineering, Sungkyunkwan University, <sup>2</sup> Department of Semiconductor Convergence Engineering, Sungkyunkwan University
FP1-016	The Study of the Effects of Cu-density and Pad Size in the CMP Process for 3D Hybrid Boding Su-Jeong Kang, Sang-Soo Kim, Won-Youl Shin, Min-Jae Kim, Sungmin Park, Dongkeun Lee, and Kyung-Ho Park Advanced Packaging TF, Korea Advanced Nano Fab Center (KANC)
FP1-017	Effect of Adhesion on Compression Fatigue Reliability of Cu Interconnect. Jun Hyeok Hyun, Min Ju Kim, Jeong A Heo, and So-Yeon Lee Department of Materials Science and Engineering, Kumoh National Institute of Technology
FP1-018	Effects of Plasma Power on Properties of SiCOH Low Dielectric Constant Films in Plasma Enhanced Chemical Vapor Deposition Process Using the Tris(trimethylsiloxy)silane Precursor Namwuk Baek <sup>1</sup> , Chanyong Seo <sup>1</sup> , Jihwan Cha <sup>1</sup> , Hyewon Han <sup>1,2</sup> , Kyubeom Bae <sup>1</sup> , Jeongbeom Choi <sup>1</sup> , Jaeyeon Kim <sup>1</sup> , and Donggeun Jung <sup>1</sup> Department of Physics, Sungkyunkwan University, <sup>2</sup> Research Laboratory, L&P Lab Co., Ltd.
FP1-019	Microwave-Reduced Graphene Oxide with Doping towards VLSI Interconnect Jaegyu Kim, Cheol-Hyeon Yoon, and Byoung Don Kong Department of Electrical Engineering, POSTECH
FP1-020	시간 및 첨가제에 따른 Through-hole via Fill 거동 연구 Eun-Bi Lee <sup>1</sup> , So-Yeon Lee <sup>1</sup> , Kyung-A Won <sup>2</sup> , and Seung-Yong Lee <sup>2</sup> <sup>1</sup> Kumoh National Institute of Technology, <sup>2</sup> LG Innotek

FP1-021	<b>3D Printing of Through-Hole-Embedded Organic Interposer Substrates</b> Guk Cho <sup>1</sup> Haksoon Jung <sup>1,2</sup> Yechan Han <sup>1</sup> Seongmin Eum <sup>1</sup> , and Jimin Kwon <sup>1</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Department of Chemical Engineering, POSTECH
FP1-022	Etch-Free Formation of Vertical Conductive Path in Silicon-Based Dielectrics for Enhanced Semiconductor Integration and Reliability Soon Joo Yoon, Jin Tae Park, and Yoon Kyeung Lee Division of Advanced Materials Engineering, Jeonbuk National University
FP1-023	Area Shrinkage 에 따른 Fringing Cap 의 BEOL 성능에 대한 영향성 분석 Seon Gyo Jang, Jun Nyeong Lee, Hye Jun Jin, Jeong Hoon Ahn, and Jong Ho Lee Foundry Business, Samsung Electronics Co., Ltd.
FP1-024	Investigation of Size-Dependent Electrical Properties in Schottky Barrier Diodes 설유진 <sup>1</sup> , 김현규 <sup>1</sup> , 황해철 <sup>1</sup> , 윤봉노 <sup>1</sup> , 남은서 <sup>1</sup> , 김정식 <sup>3</sup> , 김기현 <sup>1,2</sup> <sup>1</sup> 전북대학교 전자정보공학부, <sup>2</sup> 전북대학교 전자공학부, <sup>3</sup> 경상대학교 전기공학과
FP1-025	Effects of ALD Al <sub>2</sub> O <sub>3</sub> Layer on Interfacial Reaction of Sn-3.0Ag-0.5Cu Solder Joints Eun-Chae Noh and Jeong-Won Yoon Department of Advanced Materials Engineering, Chungbuk National University
FP1-026	Bridge-contact Resistance Method to Precisely Evaluate the Electrical Contact Characteristics of Nano-scale Semiconductor Devices Huiyun Jung, Jiyeong Yun, and Hongsik Park School of Electronic and Electrical Engineering, Kyungpook National University
FP1-027	DAF-less Chip Bonding Package Process by using Self-assembled Monolayer 김원빈 <sup>1</sup> , 최성재 <sup>1</sup> , 이선기 <sup>1</sup> , 김병준 <sup>2</sup> , 주영창 <sup>1</sup> <sup>1</sup> 서울대학교 재료공학부, <sup>2</sup> 한국공학대학교 신소재공학과
FP1-028	3차원 반도체 패키징 접합부의 기계적 신뢰성 평가 Youngju Sim, Ji-Youn Kwak, and Ju-Young Kim UNIST

FP1-029	Effect of Bending Frequency on Cu Flexible Interconnect 이선기 <sup>1</sup> , 현준혁 <sup>2</sup> , 이소연 <sup>2</sup> , 주영창 <sup>1</sup> <sup>1</sup> 서울대학교 재료공학부, <sup>2</sup> 금오공과대학교 신소재공학과
FP1-030	Enhancing Heat Dissipation in Chiplet-Based AI Semiconductors: A Comprehensive Modeling Approach Sam Yaw Anaman <sup>1</sup> , Min-Jun Cheon <sup>1</sup> , Jung-Won Lee <sup>2</sup> , Lewis Kang <sup>2</sup> , Jung Ho Kim <sup>3</sup> , Jae Yong Song <sup>4</sup> , Inhak Han <sup>5</sup> , and Hoon-Hwe Cho <sup>1</sup> <sup>1</sup> Hanbat National University, <sup>2</sup> Nepes, <sup>3</sup> Asciland, <sup>4</sup> POSTECH, <sup>5</sup> Baum
FP1-032	WBG 및 UWBG 전력반도체 모듈의 열적 성능 확인을 위한 시뮬레이션 Guesuk Lee KETI
B. Patterning (	(Lithography & Etch Technology) 분과 ZONE 1 (1층 전시장)
FP1-033	A Study on Silicon Oxide Etching with High Aspect Ratio Using the CCP- type MERIE Process Byeong-Hyeok Choi, Woong Sun Lim, Sung-Min Park, and Sang Hyun Jung Korea Advanced Nano fab Center
FP1-034	Effects of Oxygen Plasma Treatment on the Structural and Electronic Properties of MoS2 Grown by MOCVD Jiwon Heo and Taewan Kim <sup>1</sup> Department of Electrical Engineering, Jeonbuk National University, <sup>2</sup> Smart Grid Research Center, Jeonbuk National University
FP1-035	Effect of Alkaline Earth Elements on the Plasma-Resistance Properties of the Li2O-Al2O3-SiO2 Glasses for the Semiconductor Etch Process So Won Kim, Hwan Seok Lee, Deok Sung Jun, and Hee Chul Lee Tech University of Korea
FP1-036	Perfluoroalkyl Vinyl Ether의 분자구조에 따른 SiO2 식각 특성: PPVE와 PIPVE의 비교 전동준 <sup>1,2</sup> , 유상현 <sup>1,2</sup> , 김창구 <sup>1,2</sup> <sup>1</sup> Department of Chemical Engineering, Ajou University, <sup>2</sup> Department of Energy Systems Research, Ajou University

	Selective Etch of Boron-Doped Silicon Hard Mask using Chlorine-Based
	Reactive Ion Etching Process
	Sangbae Lee <sup>1</sup> , Heeju Ha <sup>1</sup> , Hojin Kang <sup>1</sup> , Hyeongwu Lee <sup>2</sup> , Minsung Jeon <sup>3</sup> , and
FP1-037	Heeyeop Chae <sup>1,2,3</sup>
TFT-037	<sup>1</sup> School of Chemical Engineering, Sungkyunkwan University, <sup>2</sup> Department of Nano
	Science and Technology, SKKU Advanced Institute of Nanotechnology (SAINT),
	Sungkyunkwan University, <sup>3</sup> Department of Semiconductor Convergence Engineering,
	Sungkyunkwan University
	Fluoro-alcohol Plasma에서 방전 가스 Chemistry에 따른 SiO2 식각 특성 비
	· 교
FP1-038	양현석 <sup>1,2</sup> , 유상현 <sup>1,2</sup> , 김창구 <sup>1,2</sup>
	<sup>1</sup> Department of Chemical Engineering, Ajou University, <sup>2</sup> Department of Energy
	Systems Research, Ajou University
	Solution Processed Bilayer Source/Drain Electrodes for High
	Performance and Stable Metal Oxide Thin-Film Transistors
FP1-039	Sungyun Kim <sup>1</sup> , Sehwan Park <sup>1</sup> , Duhyoung Gong <sup>1</sup> , Bongjun Kim <sup>2</sup> , Hanul Moon <sup>1,2</sup>
TF1-039	<sup>1</sup> Department of chemical engineering (BK21 FOUR Graduate Program), <sup>2</sup> Department
	of Semiconductors, Dong-A University, <sup>3</sup> Department of Electronics Engineering,
	Sookmyung women's University
FP1-040	EUV 마스크 용 Pt 기반 흡수 소재 식각 성능
FP1-040	김연수 <sup>1,2</sup> , 정동민 <sup>1,2</sup> , 이승호 <sup>1,2</sup> , 안진호 <sup>1,2</sup> <sup>1</sup> 한양대학교 신소재공학과, <sup>2</sup> EUV-IUCC
	한영대학교 전조제공학교, EUV-1000
	Fluorine 및 chlorine계 플라즈마 적용 유기-무기 수직분자선 다층 분자막
FP1-041	석지후 <sup>1,4</sup> , 정지우 <sup>1,4</sup> , 지현석 <sup>2</sup> , 이재혁 <sup>2</sup> , 박인성 <sup>3</sup> , 성명모 <sup>2,4</sup> , 안진호 <sup>1,4</sup>
	<sup>1</sup> 한양대학교 신소재공학과, <sup>2</sup> 한양대학교 화학과, <sup>3</sup> 한양대학교 나노과학기술연구소,
	<sup>4</sup> EUV-IUCC (Industry University Collaboration Center)
	Focus 에 따른 마스크 특성 변화 완화가 가능한 high-NA EUV 노광 공정용
FP1-042	high-k binary 마스크 연구
	이승호 <sup>1,2</sup> , 정동민 <sup>1,2</sup> , 김연수 <sup>1,2</sup> , 안진호 <sup>1,2</sup>
	- 이상도 , 88년 , 8년부 , 6년부 , 6년 - 1 1한양대학교 신소재공학과, <sup>2</sup> EUV-IUCC
FP1-043	라디칼 모듈을 이용한 Low GWP Precursor의 원자층 식각 공정
	Eun Chong Kang, Se Jun Son, Jong Hyeon Kim, Hojune Chang, and Kyong Nam Kim
	Daejeon University



FP1-044	C <sub>4</sub> H <sub>2</sub> F <sub>6</sub> 가스를 이용한 플라즈마 식각공정 및 가스 재사용에 관한 연구 Sejun Son, Eunchong Kang, Jinu Choi, Jeongwoon Bae, and Kyongnam Kim Daejeon University
FP1-045	A Study on Dry Etching Mechanism of TiN and HfO <sub>2</sub> Thin Films Ar/CF <sub>4</sub> /O <sub>2</sub> /H <sub>2</sub> -based Plasma for High-k Capacitor Process Deok-Seong Jeon, So-Won Kim, Hong-Hee Jeon, and Hee Chul Lee Department of Advanced Materials Engineering, Tech University of Korea
FP1-046	Grain Size 및 조성비에 따른 EUV 펠리클의 기계적 특성 변화 김원진 <sup>1,2</sup> , 김하늘 <sup>1,2</sup> , 강영우 <sup>1,2</sup> , 김정연 <sup>1,2</sup> , 박영욱 <sup>1,2</sup> , 안진호 <sup>1,2</sup> <sup>1</sup> 한양대학교 신소재공학과, <sup>2</sup> EUV-IUCC
FP1-047	Theoretical Study of Structural Properties and Adhesion Improvement of P(VDF-HFP) Polymers by Using Molecular Dynamics Simulation. Seung Weon Jeong <sup>1</sup> , Sangheon Lee <sup>1</sup> , and Hyung Kyu Lim <sup>2</sup> <sup>1</sup> Department of Chemical Engineering and Materials Science, Ewha Womans University, <sup>2</sup> Department of Chemical Engineering, Kangwon National University
FP1-048	Nanometer-Scale Etching of Cobalt Thin Films Using High DensityPlasma of Acetone/ArGeum Bin Baek, Kyung Ho Oh, Seung Hyun Kim, and Chee Won ChungDepartment of Chemical Engineering, Inha University
FP1-050	Atomic Layer Etching of SnO <sub>2</sub> Hyun Seo Park, Kyung Min Mo, and Ji Hye Kim ISAC Research
FP1-051	Isotropic Atomic Layer Etching of HfO2 Using NF3 Plasma and MetalPrecursorGyejun Cho, Yewon Kim, Jehwan Hong, Hye-Lee Kim, and Won-Jun LeeDepartment of Nanotechnology and Advanced Materials Engineering,Sejong University
FP1-052	플라즈마 표면 처리에 따른 유연성 기판의 AFM Force-distance 특성 연구 Juhyeon Lee, Jhongwoong Park, and Jaewook Jeong School of Information and Communication Engineering, Chungbuk National University
FP1-053	Correlation between Mask Slope and Redeposition in Cu Dry Etching Yoon Jae Cho, Su Myung Ha, and Chee Won Chung Department of Chemical Engineering, Inha University

FP1-054	Ab Initio Study of Chelation on Amorphous CoCl2 Films for Atomic Layer Etching Eugene Huh and Sangheon Lee Ewha Womans University
FP1-055	불소화 유기 단분자 극자외선 레지스트의 감도 향상 전략 김가영 <sup>1</sup> , 구예진 <sup>1</sup> , 이진균 <sup>1</sup> , 김지호 <sup>2</sup> , 박병규 <sup>2</sup> , 이상설 <sup>2</sup> , 장유하 <sup>3</sup> , 정병준 <sup>3</sup> , 고차원 <sup>4</sup> , 니시츠 네히로 <sup>4</sup> , 김현우 <sup>4</sup> <sup>1</sup> Inha University, <sup>2</sup> Pohang Accelerator Laboratory, <sup>3</sup> University of Seoul, <sup>4</sup> Samsung Electronics Co., Ltd.
FP1-056	Antimony Organometallic Photoresists for EUV Lithography Sun Jin Lee <sup>1</sup> , Dong Kyun You <sup>2</sup> , Kang Mun Lee <sup>2</sup> , and Myung-Gil Kim <sup>1</sup> <sup>1</sup> School of Advanced Materials Science and Engineering, Sungkyunkwan University, <sup>2</sup> Department of Chemistry, Institute for Molecular Science and Fusion Technology, Kangwon National University
FP1-057	Development of Environmentally Friendly Semiconductor Patterning Technology Using Supercritical Carbon Dioxide Yejin Ku <sup>1</sup> , Gayoung Kim <sup>1</sup> , Jin-Kyun Lee <sup>1</sup> , Sangsul Lee <sup>2</sup> , Byung Jun Jung <sup>3</sup> , Chawon Koh <sup>4</sup> , Tsunehiro Nishi <sup>4</sup> , Hyun-Woo Kim <sup>4</sup> <sup>1</sup> Inha University, <sup>2</sup> Pohang Accelerator Laboratory, <sup>3</sup> Korea University, <sup>4</sup> Samsung Electronics Co., Ltd.
FP1-058	The Theoretical Study of the Decomposition Mechanism of $C_2HF_5$ and $C_4F_8O$ . Mihyeon Cho and Sangheon Lee Department of Chemical Engineering and Materials Science, Ewha Womans University
FP1-059	Calculation of Decomposition Properties of Fluoro-ketone as $C_3F_6O$ Minji Kim and Sangheon Lee Chemical Engineering and Materials Science, Ewha Woman's University
FP1-060	Cryogenic Aspect Ratio Etching of SiO <sub>2</sub> Using CF <sub>4</sub> /H <sub>2</sub> /Ar Plasma in a Cryogenic Reactive Ion Etch System Hyeon Jo Kim, In Young Bang, Hee Tae Kwon, Jae Hyeon Kim, Seong Yong Lim, Seo Yeon Kim, Seong Hee Cho, Ji Hwan Kim, Woo Jae Kim, Gi Won Shin, and Gi-Chung Kwon Department of Electrical and Biological Physics, Kwangwoon University

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#### C. Material Growth & Characterization 분과

ZONE 4 (3층 로비)

FP1-061	Ferroelectricity and Phase Pure Orthorhombic Formation in PLD-grown Hf <sub>0.5</sub> Zr <sub>0.5</sub> O <sub>2</sub> MoS <sub>2</sub> Negative Capacitance Field Effect Transistors Avis Wee Sin Hui <sup>1</sup> , Pavan Pujar <sup>2</sup> , Haewon Cho <sup>3</sup> , and Sunkook Kim <sup>1</sup> <sup>1</sup> Department of Advanced Materials Science and Engineering, Sungkyunkwan University, <sup>2</sup> Indian Institute of Technology (IIT-BHU) Varanasi, <sup>3</sup> Samsung Electronics Co., Ltd.
FP1-062	Polarization Control of Photocurrent in KNiF <sub>3</sub> /BaTiO <sub>3</sub> Composite Ceramics Gwangbo Sim, Chang Won Ahn, Gu cheol Ahn, III Won Kim, and Tae Heon Kim Department of Physics and Energy Harvest-Storage Research Center (EHSRC), University of Ulsan
FP1-063	Highly Crystalline Flexible Oxide Membranes for Energy Harvesting Jiwon Kim <sup>1,2</sup> , Muhammad Sheeraz <sup>1,2</sup> , Chang Won Ahn <sup>1,2</sup> , III Won Kim <sup>1,2</sup> , and Tae Heon Kim <sup>1,2</sup> <sup>1</sup> Department of Physics, University of Ulsan, <sup>2</sup> EHSRC, University of Ulsan
FP1-064	Probing Physical Properties of ZnSnN <sub>2</sub> Grown on GaN/c-sapphire Template Using Reactive RF-sputtering Juchan Hwang <sup>1</sup> , Dohyun Kim <sup>1</sup> , Chu-Young Cho <sup>2</sup> , and Kwangwook Park <sup>1,3</sup> <sup>1</sup> Division of Advanced Materials Engineering, Jeonbuk National University, <sup>2</sup> Electronic Devices Lab, KANC, <sup>3</sup> Hydrogen and Fuel Cell Research Center, Jeonbuk National University
FP1-065	Highly Ordered Ti <sub>3</sub> C <sub>2</sub> T <sub>x</sub> MXene Film with Improved Mechanical Strength and Oxidation Resistance Colin Wing-Lok Cheng, Gang San Lee, and Sang Ouk Kim Department of Materials Science and Engineering, KAIST
FP1-066	Synthesis of Large Area MoS <sub>2</sub> for Optoelectronics by Plasma-Enhanced Chemical Vapor Deposition Mincheol Park <sup>1</sup> , Arindam Bala <sup>2</sup> , Na Liu <sup>2</sup> , Anamika Sen <sup>2</sup> , and Sunkook Kim <sup>1,2</sup> <sup>1</sup> Department of Semiconductor Convergence Engineering, Sungkyunkwan University, <sup>2</sup> Department of Advanced Materials Science and Engineering, Sungkyunkwan University

FP1-067	Synthesis of Highly c-axis Oriented VSe2 Thin Films on Si Substrates via
	a Hybrid Deposition Method
	Inhyeok Oh <sup>1</sup> , Jung-Woo Lee <sup>2</sup> , and Sanghan Lee <sup>1</sup>
	<sup>1</sup> GIST, <sup>2</sup> Hongik University
	Laser-assisted Synthesis of Multidimensional Polymorphic MoS <sub>2</sub>
FP1-068	Crystals Chanjin Kim <sup>1</sup> , Sunhwa Hong <sup>1</sup> , Seoungwoong Park <sup>2</sup> , and Byung Hee Hong <sup>1</sup>
	<sup>1</sup> Department of Chemistry, Seoul National University, <sup>2</sup> RIST
	Enhanced Remnant Polarization in TMDs-capped Hf <sub>0.5</sub> Zr <sub>0.5</sub> O <sub>2</sub> Thin Films
FP1-069	Soyeon Lee and Sanghan Lee GIST
	Analysis of $Ar/H_2S$ Inductively Coupled Plasma Reaction Using Global
	Model for MoS <sub>2</sub> Synthesis
FP1-070	Nayoon Kang <sup>1</sup> , Tae-Hyun Kim <sup>2</sup> , and Eun-Ho Lee <sup>1,2</sup>
	<sup>1</sup> Department of Mechanical Engineering, Sungkyunkwan University, <sup>2</sup> Department of Smart Fab. Technology, Sungkyunkwan University
	Energy-efficient Memcapacitor based on BiFeO3: A Feasible In-memory
FP1-071	Computing
161-071	Jiwoong Yang and Sanghan Lee
	GIST
	A Large-area Active-matrix Image Sensor based on Nanoporous MoS <sub>2</sub>
FP1-072	Phototransistors with Enhanced Photoresponsivity and Uniformity
	Myat Thet Khine <sup>1</sup> , Heekyeong Park <sup>2</sup> , Anamika Sen <sup>1</sup> , and Sunkook Kim <sup>1</sup> <sup>1</sup> Sungkyunkwan University, <sup>2</sup> Samsung Electronics Co., Ltd.
	Growth of HfSe <sub>2</sub> with in-situ BN Passivation for Improved Electrical
	Properties
FP1-073	Jung Dae Lee and Sanghan Lee
	GIST
	Exploring the Optical Defect Properties of Amorphous SiNx Using
	Spectroscopic Ellipsometry
FP1-074	Hyun Don Kim <sup>1,2</sup> , Minseon Gu <sup>1</sup> , Xuan Au Nguyen <sup>3</sup> , Junghyeon Beak <sup>1,2</sup> , Hanyeol Ahn <sup>1</sup> ,
	Tae Jung Kim <sup>3</sup> , Young Dong Kim <sup>3</sup> , Moonsup Han <sup>1</sup> , Young Jun Chang <sup>1,2,4</sup> , and E.J. Choi <sup>1</sup>
	<sup>1</sup> Department of Physics, University of Seoul, <sup>2</sup> Department of Smart Cities, University
	of Seoul, <sup>3</sup> Department of Physics, Kyung Hee University, <sup>4</sup> Department of Intelligent
	Semiconductor, University of Seoul

FP1-075	P형 Tellurium FET의 저온 특성 분석 김민재 <sup>1,2</sup> , 이용수 <sup>1,2</sup> , 김규헌 <sup>1,2</sup> , 김승모 <sup>1,2</sup> , 이해원 <sup>1,2</sup> , 전재현 <sup>1,2</sup> , 황현준 <sup>1,2</sup> , 이병훈 <sup>1,2</sup> <sup>1</sup> CSTC, POSTECH, <sup>2</sup> Department of Electrical Engineering, POSTECH
FP1-076	Highly Efficient Vertical Outgassing Channel Technique for Direct Wafer Bonding and III-V Membrane Regrowth Honghwi Park, Hosung Kim, Dong-Hun Lee, and Won Seok Han Photonic/Wireless Devices Research Division, ETRI
FP1-077	Enhancing P-Type FET Performance in WSe <sub>2</sub> via Se-vacancy Healing and Oxygen Substitution HyeonHo Jeong, Haewon Cho, Younghyun Ju, and Sunkook Kim Sungkyunkwan University
FP1-078	Engineering In-Gap States of Silicon Nitride (SiN <sub>x</sub> ) for Charge Trap Flash Memory Hanyeol Ahn <sup>1</sup> , Minseon Gu <sup>1</sup> , Hyun Don Kim <sup>1,2</sup> , Kyu-Myung Lee <sup>3</sup> , Jinwoo Byun <sup>5</sup> , Gukhyon Yon <sup>5</sup> , Yongsup Park <sup>3</sup> , E.J. Choi <sup>1</sup> , Young Jun Chang <sup>1,2,4</sup> , and Moonsup Han <sup>1</sup> <sup>1</sup> Department of Physics, University of Seoul, <sup>2</sup> Department of Smart Cities, University of Seoul, <sup>3</sup> Department of Physics, Kyung Hee University, <sup>4</sup> Department of Intelligent Semiconductor, University of Seoul, <sup>5</sup> Advanced Process Development Team, Semiconductor R&D Center, Samsung Electronics Co., Ltd.
FP1-079	Evaluation of Atomic-level Interfacial Layer Using AFM Minhyung Kim <sup>1</sup> , Jina Kim <sup>1</sup> , Yong Hyeon Cho <sup>2</sup> , Seungjae Heo <sup>1</sup> , Hu Young Jeong <sup>3</sup> , Min Hyuk Park <sup>2</sup> , and Yunseok Kim <sup>1</sup> <sup>1</sup> School of Advanced Materials Science and Engineering, SKKU, <sup>2</sup> Department of Materials Science and Engineering, SNU, <sup>3</sup> Graduate School of Semiconductor Materials and Devices Engineering, UNIST
FP1-080	Defect States of AlxGa <sub>1-x</sub> N Epilayers Grown on Si-doped GaN by Metal Organic Chemical Vapor Deposition Kyoung Su Lee <sup>1</sup> , Joocheol Jeong <sup>2</sup> , Yunseok Heo <sup>2</sup> , Okhyun Nam <sup>2</sup> , and Eun Kyu Kim <sup>1</sup> <sup>1</sup> Department of Physics and Research Institute of Natural Sciences, Hanyang University, <sup>2</sup> Department of Nano & Semiconductor Engineering, Tech University of Korea
FP1-081	Room Temperature Growth of In-plane Controllable MgO Thin Film by Off-axis Sputtering for Monolithic 3D Integration of Epi-Ge Daeyoon Baek <sup>1,2</sup> , Seung-Hwan Kim <sup>2</sup> , Seong-hyun Son <sup>1,2</sup> , Seung-heon Chris Baek <sup>2</sup> , and Hyung-jun Kim <sup>2</sup> <sup>1</sup> School of Electrical Engineering, Korea University, <sup>2</sup> Center for Spintronics, Korea Institute of Science and Technology

FP1-082	Epitaxial Growth 를 통한 Poly-Si 기판에서의 선택적 증착 특성 연구 김성준 <sup>1</sup> , 박준형 <sup>2</sup> , 정회윤 <sup>2</sup> , 신왕철 <sup>2</sup> , 박인성 <sup>3</sup> , 박영욱 <sup>2</sup> , 안진호 <sup>1,2,4</sup> <sup>1</sup> 한양대학교 나노반도체공학과, <sup>2</sup> 한양대학교 신소재공학과, <sup>3</sup> 한양대학교 나노과학기술연구 소, <sup>4</sup> EUV-IUCC(Industry University Collaboration Center)
FP1-083	Switching Control of ZnTe Layer Modulated by Bottom TiN Electrode Yeong Gwang Kim <sup>1,2</sup> , Wansun Kim <sup>3</sup> , Sang Hwa Park <sup>4</sup> , Min Jay Kim <sup>1,2</sup> , Jaeyeon Kim <sup>3</sup> , Tae Gyu Rhee <sup>1,2</sup> , In Hak Lee <sup>5</sup> , Hyuk Jin Kim <sup>1</sup> , Sang Mo Yang <sup>4</sup> , Hyunchul Sohn <sup>3</sup> , Young Jun Chang <sup>1,2</sup> , <sup>6</sup> <sup>1</sup> Department of Physics, University of Seoul, <sup>2</sup> Department of Smart Cities, University of Seoul, <sup>3</sup> Department of Material Science and Engineering, Yonsei University, <sup>4</sup> Department of Physics, Sogang University, <sup>5</sup> Department of Physics, UC Berkeley, <sup>6</sup> Department of Intelligent Semiconductor Engineering, University of Seoul
FP1-084	Fabrication of Fe-MST Memory with Van Der Waals Heterostructure based on Characteristics of Ferroelectric HZO and Ferroelectric-phase Transition Material Do Kyeong Yun and Woo Jong Yu Department of Electrical and Computer Engineering, Sungkyunkwan University
FP1-085	Observation of Ferroelectric Phase Transitions in Two-dimensional Hybrid Organic Inorganic Perovskites through Piezoresponse Force Microscopy Tae Hyun Jung <sup>1</sup> , Yun Seung Kuk <sup>2</sup> , Sang Woo Lee <sup>1</sup> , Kang Min Ok <sup>2</sup> , and Sang Mo Yang <sup>1</sup> <sup>1</sup> Department of Physics, Sogang University, <sup>2</sup> Department of Chemistry, Sogang University
FP1-086	New Volatile Strontium Precursors for Next Generation Capacitor in DRAM Chanwoo Park <sup>2</sup> , Chang Seop Hong <sup>1</sup> , and Taek-Mo Chung <sup>2</sup> <sup>1</sup> Department of Chemistry, Korea University, <sup>2</sup> Advanced Materials Division, KRICT
FP1-087	Strain Effect on the Ferroelectric Domain Morphology in Rhombohedral Multilayer Molybdenum Disulfide June Hee Shin, Sae-A Kim, and Sang Mo Yang Department of Physics, Sogang University
FP1-088	Post-heat Treatment Effect of Tin Monosulfide Synthesized by Metal Organic Chemical Vapor Deposition Ji Woon Choi <sup>1</sup> and Taek-Mo Chung <sup>1,2</sup> <sup>1</sup> Thin Film Materials Research Center, KRICT, <sup>2</sup> Department of Chemical Convergence Materials, UST

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FP1-089	Si-assisted Growth of Multilayer h-BN on Ge Seung-Hwa Baek <sup>1,2</sup> , and Cheol-Joo kim <sup>1,2</sup> <sup>1</sup> Departmet of Chemical Engineering, POSTECH, <sup>2</sup> Center or Van der Waals Quantum Solids, IBS
FP1-090	Growth of Amorphous BN Using Chemical Vapor Deposition to Find an Optimum Growth Condition Jun Sun Son and Woo Jong Yu Department of Electrical and Computer Engineering, Sungkyunkwan University
FP1-091	도핑 제어된 전이금속 WSe2/MoS2 이종 접합 포토 다이오드 Sung Hyun Kim and Woo Jong Yu Department of Electrical and Computer Engineering, Sungkyunkwan University

#### E. Compound Semiconductors 분과

ZONE 4 (3층 로비)

FP1-092	Growth of Hexagonal-shape Si Epilayer on 4H-SiC Using Mixed-source
	HVPE
	Seonwoo Park <sup>1</sup> , Suhyun Mun <sup>1</sup> , Kyoung Hwa Kim <sup>1</sup> , Hyung Soo Ahn <sup>1</sup> , Jae Hak Lee <sup>1,2</sup> ,
	Min Yang <sup>1</sup> , Young Tea Chun <sup>1</sup> , Sam Nyung Yi <sup>1</sup> , Yeon-Suk Jang <sup>3</sup> , Won Jae Lee <sup>3</sup> ,
	Myeong-Cheol Shin <sup>4</sup> , and Sang-Mo Koo <sup>4</sup>
	<sup>1</sup> Department of Nano-Semiconductor Engineering, Korea Maritime and Ocean
	University, <sup>2</sup> LNBS Co., Ltd., <sup>3</sup> Department of Advanced Materials Engineering, Dong-
	Eui University, <sup>4</sup> Department of Electronic Materials Engineering, Kwangwoon
	University
	Growth of Ge-AIN Hexa-cone Core-shell Microneedles by AIN Nanowires
FP1-093	Suhyun Mun <sup>1</sup> , Seonwoo Park <sup>1</sup> , Kyoung Hwa Kim <sup>1</sup> , Hyung Soo Ahn <sup>1</sup> , Jae Hak Lee <sup>1,2</sup> ,
	Min Yang <sup>1</sup> , Young Tea Chun <sup>1</sup> , Sam Nyung Yi <sup>1</sup> , Yeon-Suk Jang <sup>3</sup> , Won Jae Lee <sup>3</sup> ,
	Myeong-Cheol Shin <sup>4</sup> , and Sang-Mo Koo <sup>4</sup>
	<sup>1</sup> Department of Nano-Semiconductor Engineering, Korea Maritime and Ocean
	University, <sup>2</sup> LNBS Co., Ltd., <sup>3</sup> Department of Advanced Materials Engineering, Dong-
	Eui University, <sup>4</sup> Department of Electronic Materials Engineering, Kwangwoon
	University

FP1-094	Design and Analysis of Multiple Fin-type Vertical GaN Power Device
	based on Epitaxially Grown GaN-on-sapphire
	Jeong Woo Hong, Sang Ho Lee, Jin Park, Ga Eon Kang, Jun Hyeok Heo, So Ra Jeon,
	Min Seok Kim, Seung Ji Bae, and In Man Kang
	School of Electronic and Electrical Engineering, Kyungpook National University
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	Transistors by Adjusting Recessed Source-connected Field-plate: A
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	Ji-Hun Kim, Jae-Hun Lee, and Hyun-Seok Kim
	Division of Electronics and Electrical Engineering, Dongguk University
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	Electron Mobility Transistors (mHEMTs)
FP1-096	Jae-Phil Shim <sup>1</sup> , Hyunchul Jang <sup>1</sup> , Ki-Yong Shin <sup>1</sup> , Yongeun Kim <sup>1</sup> , Geunuk Han <sup>1</sup> , Yunji
	Jeong <sup>1</sup> , Myungsoo Park <sup>1</sup> , Seung Heon Shin <sup>2</sup> , Donghyun Kim <sup>1</sup> , and Chan-Soo Shin <sup>1</sup>
	<sup>1</sup> KANC, <sup>2</sup> Korea Polytechnics
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	Department of Nano-Semiconductor Engineering, Korea Maritime and Ocean
	University
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	Performance Power Devices
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	Seongbin Lim <sup>1</sup> , Minah Park <sup>1</sup> , Peide D. Ye <sup>2</sup> , and Hagyoul Bae <sup>1</sup>
	<sup>1</sup> Jeonbuk National University, <sup>2</sup> Purdue University
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	Jihyun Kim and Jungwan Cho
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	Electronic Material Engineering, Korea Maritime and Ocean University

	Effect of Ramp Rates of Oxidation Temperature on the Characteristics of
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	Young Jae Park <sup>1</sup> , Seongjun Kim <sup>1</sup> , Joon Kim <sup>2</sup> , Hyeon Ju Hwang <sup>1</sup> , Yu Jeong Lee <sup>1</sup> ,
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FP1-TUT	Hwan Kang <sup>1,3</sup> , and Hoon-Kyu Shin <sup>1</sup>
	<sup>1</sup> National Institute for Nanomaterials Technology, POSTECH, <sup>2</sup> Center for
	Semiconductor Technology Convergence, POSTECH, <sup>3</sup> Department of Semiconductor
	Engineering, POSTECH
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	step Metamorphic Buffer Using MOCVD
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	Jeong <sup>1</sup> , Seung Heon Shin <sup>2</sup> , Sooseok Kang <sup>1</sup> , Keun Man Song <sup>1</sup> , Yongsu Choi <sup>1</sup> ,
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	<sup>1</sup> KANC, <sup>2</sup> Korea Polytechnics
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	Yeon Hak Mu and Jae Cheol Shin
	동국대학교 전자전기공학부
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	Improving Breakdown Voltage
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	Jinhun Kim <sup>1</sup> , Gukhwa Jeon <sup>1</sup> , Sumin Park <sup>1</sup> , Dusan Baek <sup>1</sup> , Kanghee Shin <sup>1</sup> , Jaejin
	Song <sup>2</sup> , Jeongyun Lee <sup>2</sup> , Soontak Kwon <sup>2</sup> , and Ogyun Seok <sup>1</sup>
	<sup>1</sup> Kumoh National Institute of Technology, <sup>2</sup> KEC
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	Engineering and <sup>3</sup> semiconductor system engineering , Sejong University
	P형 물질의 홀 농도에 따른 D-Mode GaN HEMT 문턱전압 연구
	P영 철글의 을 응도에 따른 D-Mode Gan HEMT 문극전급 전구 Hyun-Ho Jeong <sup>1</sup> , Hyeon-Young Jeong <sup>1</sup> , Hyeon-Cheol Kim <sup>1</sup> , Sakhone Pharkphoumy <sup>1</sup> ,
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	<sup>1</sup> School of Electronic and Electrical Engineering, Kyungpook National University, <sup>2</sup> ETRI
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	School of Electronic and Electrical Engineering, Hongik University
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	Phosphors for NUV-LED Applications
FP1-121	Heonji Ha <sup>1</sup> , Jeonghun Lee <sup>2</sup> , and Sangmoon Park <sup>1,2,3</sup>
FFIFIZI	<sup>1</sup> Department of Electronics-Energy Materials, Silla University, <sup>2</sup> Division of Energy and
	Chemical Engineering Major in Energy and Applied Chemistry, Silla University,
	<sup>3</sup> Department of Fire Protection and Safety Management, Silla University
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	Doyoung Yuk <sup>1</sup> , Wook kim <sup>1</sup> , Younghan Yook <sup>1</sup> , Sujong Kim <sup>1</sup> , Minseong Seo <sup>1</sup> , Haoyan
	Rong <sup>1</sup> , Sangin Kim <sup>1,2</sup> , and Jaejin Lee <sup>1,2</sup> <sup>1</sup> Department of Intelligence Semiconductor Engineering, Ajou University, <sup>2</sup> Department
	of Electrical and Computer Engineering, Ajou University



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FP1-130	Numerical Analysis of Warpage by HBM Structure during Hybrid Bonding Seong-Hwan Park and Eun-Ho Lee Sungkyunkwan University
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FP1-132	Efficient Improvements of Poly-Based Resistor Variation Employing Implantation Impact for Achieving High Yield of Mobile Display Driver IC Myeonghwan Kim, Jooyeok Seo, Dong-Il Park, Youngmok Kim, Kyunglyong Kang, Jun-gu Kang, and Yongsang Jeong Foundry Division, Samsung Electronics Co., Ltd.
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FP1-140	Local Plasma Treatment Effect on TMD Device Analyzed by DC and LFN Jiyoon Kim <sup>1</sup> , Yonghun Kim <sup>2</sup> , and Hyunjin Ji <sup>1</sup> <sup>1</sup> Department of Electrical Engineering, University of Ulsan, <sup>2</sup> Department of Energy & Electronic Materials, KIMS
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FP1-142	Finite-bias Molecular Dynamics Simulations of Water at the Electrified Graphene Surface Hyeonwoo Yeo, Juho Lee, Ryong Gyu Lee, and Yong-Hoon Kim School of Electrical Engineering, KAIST
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FP1-145	Study on Leakage Current and Scaling Limit of Cell Transistor Gate Oxide in DRAM for TDDB Reliability Ji hye Kwon, Pyung Moon, Myeong jin Bang, Dong sik Gong, Kyul Ko, Jun bum Lee, Jea hyun Choi, Jun soo Kim, Jeong hoon Oh, II gweon Kim, Je min Park, and Jai hyuk Song Samsung Electronics Co., Ltd.
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FP1-154	Ising Machine based on Ovonic Threshold Switch Oscillator Young Woong Lee <sup>1</sup> , Unhyeon Kang <sup>1,3</sup> , Sangheon Kim <sup>1,2</sup> , Seungmin Oh <sup>1,3</sup> , Jaewook Kim <sup>1,3</sup> , Daseung Jeong <sup>1</sup> , Jingyeong Hwang <sup>1</sup> , and Suyoun Lee <sup>1,5</sup> <sup>1</sup> Center for Neuromorphic Engineering, KIST, <sup>2</sup> Department of Materials Science and Engineering, Korea University, <sup>3</sup> Materials Science & Engineering, Seoul National University, <sup>4</sup> Department of Materials Science & Engineering, Seoul National University of Science and Technology, <sup>5</sup> Division of Nano & Information Technology, Korea University of Science and Technology
FP1-155	First-principles Study of Gating-Based Modulation Defect Energy Levels in Hexagonal Boron Nitride on MoS <sub>2</sub> Ji-Yoon Song, Ryong-Gyu Lee, and Yong-Hoon Kim School of Electrical Engineering, KAIST
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FP1-158	Strain & Low-temperature Behavior of Quantum Hybridization Negative Differential Resistance from Non-Pb 1D Halide Perovskite Jeongwon Lee, Tae Hyung Kim, Juho Lee, and Yong-Hoon Kim School of Electrical Engineering, KAIST
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FP1-164	Investigation of Contact Resistance between WO <sub>x</sub> Channel and Metal Electrodes in Electrochemical Random-Access Memory Juhee Kim, Junyoung Choi, Seungkun Kim, Hyunjeong Kwak, and Seyoung Kim Department of Materials Science and Engineering, POSTECH
FP1-165	Whole-Chip All-Directional ESD Protection Circuit with SCR Structure for Low Voltage Applications Bo-Bae Song, Young-chul Kim, and Hyun-chul Nah Device Enabling Team, DB HiTek

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FP1-167	Extraction of Subgap Density-of-States in AOS TFTs through Capacitance-Voltage Characteristics Considering Photovoltaic Effect Sueng Hyeop Han, Haesung Kim, Ju Young Park, Jong-Ho Bae, Sung- Jin Choi, Dae Hwan Kim, and Dong Myong Kim Kookmin University
FP1-168	Quantitative Modeling of the Endurance Degradation in NAND FlashMemoryHan Byeol Oh and Byung Chul JangSchool of Electronic and Electrical Engineering, Kyungpook National University
FP1-169	Breakdown Voltage Improvement in Junction Isolation Type LDMOS Sin Wook Kim, Dong Yeong Kim, Su Yeon Kim, Je Won Park, Chae Hyuk Lim, and Myoung Jin Lee Department of ICT Convergence System Engineering, Chonnam National University
FP1-170	Switching Performance Improvements of RRAM by Applying Protruding Top Electrode and Utilizing Surface Roughness: Multi-physics Simulations Jeonghwan Jang and Mincheol Shin School of Electrical Engineering, KAIST
FP1-171	Development of High Voltage ESD Lateral PNP with Base External Resistor and NWELL Cut-out Young Sang Son, Young Chul Kim, and Jong Min Kim Technology Enabling Design Support Team, DB HiTek
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	TFT with Different Source/Drain Metal
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	Jin Choi, Dae Hwan Kim, Dong Myong Kim, and Jong-Ho Bae
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	Analysis on Drain Current Transient Response in Amorphous $InGaZnO_x$
	Thin-Film Transistors
FP1-174	Yubin Choi, Haesung Kim, Hyojin Yang, Sejun Park, Junseong Park, Sung-Jin Choi,
	Dae Hwan Kim, Dong Myong Kim, and Jong-Ho Bae
	School of Electrical Engineering, Kookmin University
	3D Simulation Study of an Edge Termination for Improving Breakdown
	Characteristics
FP1-175	Jee Hun Jeong, Min Seok Jang, Da Hui Yoo, Jung Bok Lee <sup>1</sup> , and Ho Jun Lee
	Pusan National University
	D-mode Short Circuit Failure Simulation of Silicon IGBT
	Da Hui Yoo <sup>1</sup> , Jee Hun Jeong <sup>1</sup> , Min Seok Jang <sup>1</sup> , Jung Bok Lee <sup>1</sup> , Won Seok Kwon <sup>2</sup> , and
FP1-176	Ho Jun Lee <sup>1</sup>
	<sup>1</sup> Pusan National University, <sup>2</sup> TRinno Technology Co., Ltd.
	Ar/CF4 플라즈마 식각 공정 내 물리적 스퍼터링에서 화학적 스퍼터링으로의
	전이에 따른 고종횡비 SiO2 식각 프로파일 변화에 대한 전산모사 연구
FP1-177	최병엽 <sup>1</sup> , 김시준 <sup>2</sup> , 정원녕 <sup>1</sup> , 이영석 <sup>2</sup> , 성인호 <sup>1</sup> , 조철희 <sup>1</sup> , 최민수 <sup>1</sup> , 설유빈 <sup>2</sup> , 이우빈 <sup>1</sup> ,
	서성현 <sup>1</sup> , 유신재 <sup>1,2</sup>
	<sup>1</sup> Department of Physics, Chungnam National University, <sup>2</sup> Institute of Quantum System
	(IQS), Chungnam National University
	Analysis of Silicon RC-IGBT for Improving Forward Voltage with Backside
	Processing
FP1-178	Jung Bok Lee <sup>1</sup> , Jee Hun Jeong <sup>1</sup> , Da Hui Yoo <sup>1</sup> , Min Seok Jang <sup>1</sup> , Jun Seong Kim <sup>2</sup> , and
	Ho Jun Lee <sup>1</sup>
	<sup>1</sup> Pusan University, <sup>2</sup> TRinno Technology Co., Ltd.
	Impact of Atomic Arrangements in Te-Based Binary Ovonic Threshold
FP1-179	Switches during Switching Process in Local Biasing System
	Young-Min Kim <sup>1,2</sup> , Su-Bong Lee <sup>1</sup> , Sangyeop Kim <sup>1,2</sup> , and Jong-Souk Yeo <sup>1</sup>
	<sup>1</sup> School of Integrated Technology, College of Computing, Yonsei University, <sup>2</sup> BK21
	Graduate Program in Intelligent Semiconductor Technology

H. Display and	Imaging Technologies 분과
	ZONE 1 (1층 전시장)
	Study of Transparent Conductive Oxide through Electrical and Optical
	Properties of SrRuO <sub>3</sub> Deposited on Glass and PET Substrates
FP1-180	Seung Woo Baek <sup>1</sup> , Jun Hyeok Byeon <sup>1</sup> , Ahn Hyung Soo <sup>1</sup> , Jang Nak Won <sup>1</sup> , Ji-Hoon
	Ahn <sup>2</sup> , and Hong Seung Kim <sup>1</sup>
	<sup>1</sup> Korea Maritime and Ocean University, <sup>2</sup> Hanyang University ERICA
	Near-Infrared Quantum Efficiency Improvement via Process
	Optimazation for CIS Application
FP1-181	Suhye Park, So-Yun Kim, Hyun Yoo, Nam Yoon Kim, Hyo Sik Kim, Young-Ju Lee,
	Chang Ki Lee, Keun Hyuk Lim, Jun ho Won, and Won Ho Lee
	SK hynix system ic Inc.
	Polymer Light-emitting Diodes by using 3PTZ and 3PXZ Small Molecular
FP1-182	Hole-transport Layer
FP 1-102	Ji-Yeon Kim <sup>1</sup> , Ju Hee You <sup>1</sup> , Seok Ho Seo <sup>1</sup> , and Dong Ick Son <sup>1,2,3</sup> <sup>1</sup> Institute of Advanced Composite Materials, KIST, <sup>2</sup> KIST School, UST, <sup>3</sup> Department of
	Nanomaterials and Nano Science, UST
	A Study on the Drain Induced Barrier Lowering of IGO TFT Using TCAD
FP1-183	Simulation
	Seon Woong Bang and Jae Kyeong Jeong Deptartment of Electronic Engineering, Hanyang University
	HZO-based Ferroelectric FET Using Oxide Semiconductor
FP1-184	He Young Kang and Jae Kyeong Jeong
	Department of Electronic Engineering, Hanyang University
	Enhancing IGZO/Quantum-dots Broadband Photo Sensor through Ga <sub>2</sub> O <sub>3</sub>
	Passivation Layer
FP1-185	Yongjun Jeong and JaeKyeong Jeong
	Deptartment of Electronic Engineering, Hanyang University
	Wavy Structure-based Thin-Film Transistor for Stretchable Displays
FP1-186	Jeong Eun Oh and Jae Kyeong Jeong
	Dept. of Electronics Engineering, Hanyang University
	Bifunctional Solution-processed Thin Film Transistors with Organic
FP1-187	Dielectrics for High Performance and Stability
	Min Ki Kim, Seung Yeon Koh, Hwa Pyeong Noh, Hyo Won Jang, Swarup Biswas, and
	Hyeok Kim
	School of Electrical and Computer Engineering, University of Seoul

FP1-188	Comparative Study of 3-D Field-Effect-Transistors with Indium-Gallium- Zinc Oxide Channel by TCAD Simulation Yena Kim and Jae Kyeong Jeong Department of Electronic Engineering, Hanyang University
FP1-189	Optimization of HfxZr <sub>1-x</sub> O <sub>2</sub> ferroelectric field-effect transistors by IGZO channel oxygen vacancy control Kyong Jae Kim <sup>2</sup> , Eun Seo Jo <sup>2</sup> , and You Seung Rim <sup>1,2</sup> <sup>1</sup> Department of Intelligent Mechatronics Engineering and Convergence Engineering for Intelligent Drone, Sejong University, <sup>2</sup> Department of Semiconductor Systems Engineering and Institute of Semiconductor and System IC, Sejong University
FP1-190	Facile Fabrication of Strain-Insensitive Capacitive Touch Sensor forStretchable DisplaysGeonoh Choe and Yei Hwan JungDepartment of Electronic Engineering, Hanyang University
FP1-191	Hybrid PDMS Stamp for Micro-LED Transfer Seol Ahn and Yei Hwan Jung Department of Electronic Engineering, Hanyang University
FP1-192	Transparent Red OLED Using AZO-Ag-AZO Electrode as Anode Yong Hyeok Seo <sup>1</sup> , Won Woo Lee <sup>1</sup> , Dongwoon Lee <sup>1</sup> , Dong Gyun Kim <sup>1</sup> , Young Woo Kim <sup>1</sup> , Minseong Park <sup>2</sup> , Ye Ji Shin <sup>2</sup> , Yongmin Jeon <sup>2</sup> , Sang Jik Kwon <sup>1</sup> , and Eou-Sik Cho <sup>1</sup> <sup>1</sup> Department of Electronic Engineering, Gachon University, <sup>2</sup> Department of Biomedical Engineering, Gachon University
FP1-193	Rapid Photonic Curing Effects of Xenon Flash Lamp on Sputtered AZO- Ag-AZO Multilayer TCO Films Yong Hyeok Seo <sup>1</sup> , Won Woo Lee <sup>1</sup> , Dong Gyun Kim <sup>1</sup> , Kirak Kim <sup>1</sup> , Yongmin Jeon <sup>2</sup> , Sang Jik Kwon <sup>1</sup> , and Eou-Sik Cho <sup>1</sup> <sup>1</sup> Department of Electronic Engineering, Gachon University, <sup>2</sup> Department of Biomedical Engineering, Gachon University
FP1-194	Vacancy Engineering of Copper Iodide Semiconductor for High- performance p-Type Thin-film Transistors Hyun-Ah Lee <sup>1</sup> , Hyo-Won Jang <sup>1</sup> , Tae In Kim <sup>2</sup> , Ick-Joon Park <sup>3</sup> , and Hyuck-In Kwon <sup>1</sup> <sup>1</sup> Chung-Ang University, <sup>2</sup> Inha University, <sup>3</sup> Joongbu University

FP1-195	Influence of Oxygen Content on Output Characteristics of IGZO TFTs during High Current Operation Chae-Eun Oh <sup>1</sup> , Dong-Ho Lee <sup>1</sup> , Myeong-Ho Kim <sup>2</sup> , Kyoung Seok Son <sup>2</sup> , Jun-Hyung Lim <sup>2</sup> , Sang-Hun Song <sup>1</sup> , and Hyuck-In Kwon <sup>1</sup> <sup>1</sup> Chung-Ang University, Korea, <sup>2</sup> Samsung Display
FP1-196	Effects of Al <sub>2</sub> O <sub>3</sub> Surface Passivation on the Radiation Stability of IGTO Thin Film Transistors under High-Energy X-ray Irradiation Hyun-Ah Lee <sup>1</sup> , Hyo-Won Jang <sup>1</sup> , Kie Yatsu <sup>1</sup> , Ick-Joon Park <sup>2</sup> , and Hyuck-In Kwon <sup>1</sup> <sup>1</sup> Chung-Ang University, <sup>2</sup> Joongbu University
FP1-197	A Study on the Incorporation Behavior of In, Ga, and Zn in IGZO Thin Films according to Sub-Cycle Ratio during Thermal Atomic Layer Deposition Hanseok Jeong <sup>1</sup> , Soo Min Yoo <sup>1</sup> , Minki Choe <sup>2</sup> , In-Hwan Baek <sup>2</sup> , and Woojin Jeon <sup>1</sup> <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, and Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University, <sup>2</sup> Department of Chemical Engineering, Inha University
FP1-198	High-Performance p-Type Tellurium Thin Film Transistors with Organic- Inorganic Hybrid Passivation Layer Jong-Sang Oh <sup>1</sup> , Joon-Young Lee <sup>1</sup> , Seung-Hyun Lim <sup>1</sup> , Tae In Kim <sup>2</sup> , Ick-Joon Park <sup>3</sup> , and Hyuck-In Kwon <sup>1</sup> <sup>1</sup> Chung-Ang University, Korea, <sup>2</sup> Inha University, <sup>3</sup> Joongbu University
FP1-199	TFT Off Current Stabilization Method : Using Machine Learning ANN Won Woo Lee <sup>1</sup> , Hyun Woo Kim <sup>1</sup> , Yong Hyeok Seo <sup>1</sup> , Yun Hyeok Jeong <sup>1</sup> , Yongmin Jeon <sup>2</sup> , Sang Jik Kwon <sup>1</sup> , Zong Woo Geem <sup>3</sup> , and Eou-Sik Cho <sup>1</sup> <sup>1</sup> Department of Electronic Engineering, Gachon University, <sup>2</sup> Department of Biomedical Engineering, Gachon University, <sup>3</sup> Department of Smart City, Gachon University
FP1-200	Surface Pre-treatment in Molybdenum Disulfide Atomic Layer Deposition for Next-generation Channel Materials Soo Min Yoo <sup>1</sup> , Hanseok Jeong <sup>1</sup> , Minki Choe <sup>2</sup> , In-Hwan Baek <sup>2</sup> , and Woojin Jeon <sup>1</sup> <sup>1</sup> Department of Advanced Materials Engineering for Information and Electronics, and Integrated Education Program for Frontier Science & Technology (BK21 Four), Kyung Hee University, <sup>2</sup> Department of Chemical Engineering, Inha University

554 004	Effects of Channel Width on Electrical Performance Degradation in IGZO
	TFTs under Self-heating Stresses
FP1-201	Dong-Ho Lee <sup>1</sup> , Jin-Ha Hwang <sup>1</sup> Myeong-Ho Kim <sup>2</sup> , Kyoung Seok Son <sup>2</sup> , Jun-Hyung
	Lim <sup>2</sup> , Sang-Hun Song <sup>1</sup> , and Hyuck-In Kwon <sup>1</sup>
	<sup>1</sup> Chung-Ang University, <sup>2</sup> Samsung Display
	Enhancing Stability of CsPbBr3 Perovskite Quantum Dots via Atomic
	Layer Deposition for Light-Emitting Diodes
FP1-202	Min Ju Kim <sup>1</sup> , Ju Young Woo <sup>2</sup> , and Seong-Yong Cho <sup>1</sup>
	Department of Photonics and Nanoelectronics, Hanyang University, <sup>2</sup> Digital
	Transformation R&D Department, KITECH
	Self-Assembled Monolayer에 의한 금속-산화물 반도체 사이의 Metal Oxide
	형성 억제와 접촉 저항 개선
FP1-203	Dowan Kang <sup>1</sup> , Juyoung Yun <sup>1</sup> , and Yoonyoung Chung <sup>1,2,3</sup>
11 1 205	<sup>1</sup> Department of Electrical Engineering, POSTECH, <sup>2</sup> Department of Semiconductor
	Engineering, POSTECH, <sup>3</sup> Center for Semiconductor Technology Convergence,
	POSTECH
	Device Feasibility and Process Optimization of Atomic-Layer Deposited
	AI Doped ZnO Thin Films as Electrodes for Oxide TFT Applications
FP1-204	Ye-Jin Seo <sup>1</sup> , Young-Ha Kwon <sup>2</sup> , Nak-Jin Seong <sup>2</sup> , Kyu-Jeong Choi <sup>2</sup> , and Sung-Min
	Yoon <sup>1</sup>
	<sup>1</sup> Kyung Hee University, <sup>2</sup> NCD Co., Ltd.
	Ligand-Exchanged NiO Nanoparticles as a Hole Injection Layer of
	Quantum Dot LED
	Hyojun Lim <sup>1</sup> , Thi Huong Thao Dang <sup>1</sup> , Nayoon Lee <sup>1</sup> , Sunwoo Jin <sup>1</sup> , Van Khoe Vo <sup>1</sup> , Joon-
FP1-205	Hyung Lee <sup>1</sup> , Byoung-Seong Jeong <sup>2</sup> , and Young-Woo Heo <sup>1</sup>
	<sup>1</sup> School of Materials Science and Engineering Kyungpook National University,
	<sup>2</sup> Department of Hydrogen and Renewable Energy Kyungpook National University
	Improved Light Extraction Efficiency and Color Control in Quantum Dot
FP1-206	
	LEDs Using Metal-Insulator-Metal (MIM) Structure
	Eun Sang Lee <sup>1</sup> , Hyuntai Kim <sup>2</sup> , and Seong-Yong Cho <sup>1</sup>
	<sup>1</sup> Department of Photonics and Nanoelectronics, Hanyang University, <sup>2</sup> Department of
	Electronic and Electrical Convergence Engineering, Hongik University

	Enhanced QLED Performance through Improved Charge Balance Using
	Doped NiO as the Hole Injection Layer. Nayoon Lee <sup>1</sup> , Hyojun Lim <sup>1</sup> , Van Khoe Vo <sup>1</sup> , Thi Huong Thao Dang <sup>1</sup> , Byoung-Seong
FP1-207	Jeong <sup>2</sup> , Joon-Hyung Lee <sup>1</sup> , and Young-Woo Heo <sup>1</sup>
	<sup>1</sup> School of Materials Science and Engineering, Kyungpook National University,
	<sup>2</sup> Department of Hydrogen and Renewable Energy, Kyungpook National University
	A Study on the Logarithmic Sensitivity of X-ray Detectors with Multiple
FP1-208	Pinning Voltages
11 1 200	Du Hee Lee, Nak won Yu, Jong Min Kim, and Hyun Chul Nah
	Device Enabling Team, DB HiTek
	Improvement of Uniformity on Spray-printed Organic Electrochemical
FP1-209	Transistors with Thermally-assisted Reformation
	Dongyeol Seo, Donguk Kim, and Felix Sunjoo Kim
	School of Chemical Engineering and Materials science, Chung-Ang University
	Demonstration of Vertically Stacked Dual-color Micro-LED Using CMOS-
	compatible Monolithic 3D Integration Technology for Ultra-high
FP1-210	Resolution Display
	Hyunsu Kim, Juhyuk Park, Woo Jin Baek, and SangHyeon Kim
	School of Electrical Engineering, KAIST
	Metal Ion-Doped Metal-Oxide Dielectric and Semiconducting Films for
FP1-211	Low-Voltage Operating Thin-Film Transistors
	Se-Ryong Park, Sang-Joon Park, and Tae-Jun Ha
	Department of Electronic Materials Engineering, Kwangwoon University
	Resistive Random-access Memory Properties for Cu <sub>2</sub> CoSnS <sub>4</sub> Films on
	the ITO Glass via Direct Spin-coating Process
FP1-212	Seo-young Jo, Taewon Jin, Gyubeen Kim, Yujin Choi, and Sung Hun Jin
	Department of Electronic Engineering, and I-Nanofab Center, Incheon National University
	Low-Cost, Spin-On Dopant Based N-type MOSFET Implementation for
FP1-213	Active Matrixed Micro-Light-Emitting Diode Display Operation
	Hanmin Kim, Hogeon Jeon, Chaeyeong Kim, Taeyeon Lee, Changsoo Park, and
	Sung Hun Jin Department of Electronic Engineering, and I-Nanofab Center, Incheon National
	University



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FP1-214	Monolithic Integration of p-GaN/AlGaN/GaN Driving IC for Active-Matrix Micro-LEDs Hee Jae Oh, Jun Hyeok Lim, and Ho Young Cha Hongik University
FP1-215	Solvent Dependency on Copper-lodide Film Formation via Dip-Coating and Their RRAM Properties
	Geun Lee, Da Han Lee, Tae Won Jin, Jong Gon Lee, Woo In Kim, and Sung Hun Jin Department of Electronic Engineering, and I-Nanofab Center, Incheon National University

J. Nano-Science & Technology 분과

ZONE 1 (1층 전시장)

FP1-216	Bismuth Doping Strategies in GeTe to Enhance Phase-change Transition Chang Woo Lee <sup>1</sup> , Hyeonwook Lim <sup>1</sup> , Yeonwoo Seong <sup>1</sup> , and Mann-Ho Cho <sup>1,2</sup> <sup>1</sup> Department of Physics, Yonsei University, <sup>2</sup> Department of System Semiconductor Engineering, Yonsei University
	Selective Synthesis of Atomically-thin Semiconducting Materials and Its
	Electronics Applications
FP1-217	Seoungwoong Park <sup>1</sup> , Han Duk Song <sup>1</sup> , Suk Yong Jung <sup>1</sup> , Junwoo Kim <sup>1</sup> , Jaekwang Song <sup>2</sup> , and Chan-Jin Kim <sup>3</sup>
	<sup>1</sup> RIST, <sup>2</sup> Samsung Electronics Semiconducting R&D Center, <sup>3</sup> Seoul National University
	Performance Enhancement of $MoS_2$ Transistor based on Metallic $NbS_2$
	as a Local Bottom Gate Electrode
FP1-218	Hyun Young Seo <sup>1</sup> and Byungjin Cho <sup>1,2</sup>
	<sup>1</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National
	University, <sup>2</sup> Department of Advanced Material Engineering, Chungbuk National
	University
	Electrochemical Doping of Metal Halide Perovskites
	Yongjin Kim <sup>1</sup> , Dohyun Kim <sup>1</sup> , Eunje Park <sup>1</sup> , Jeongjae Lee <sup>2</sup> , Takhee Lee <sup>3</sup> , and Keehoon
FP1-219	Kang <sup>1</sup>
11 1 2 13	<sup>1</sup> Department of Materials Science and Engineering, Seoul National University, <sup>2</sup> School
	of Earth and Environmental Sciences, Seoul National University, <sup>3</sup> Department of
	Physics and Astronomy, Seoul National University

FP1-220	MoS <sub>2</sub> Field Effect Transistor with Graphene-embedded Al <sub>2</sub> O <sub>3</sub> Gate Dielectric Structure Eunjeong Cho <sup>1,2</sup> and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Advanced Material Engineering, Chungbuk National University, <sup>2</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University
FP1-221	Molecular Level Modulation by Electrolyte Gating in Mixed SAM Molecular Vertical Junctions Donguk Kim, Changjun Lee, Minwoo Song, Jongwoo Nam, Hyemin Lee, and Takhee Lee Department of Physics and Astronomy, Seoul National University
FP1-222	Exploring the Impact of Dimensional Engineering on the Reliability and Performance of Metal Halide Perovskite Field-Effect Transistors Hyeonmin Choi, Joonha Jung, Yongjin Kim, Taehyun Kong, and Keehoon Kang Department of Materials Science and Engineering, Seoul National University
FP1-223	Human-muscle-inspired Single Fibre Actuator with Reversible Percolation Kee Woong Oh, In Ho Kim, and Sang Ouk Kim Department of Materials Science & Engineering, KAIST
FP1-224	High Rate and Large Capacity Supercapacitors by Three-dimensional Shape Engineering, Interfacial Gelation of Reduced Graphene Oxide S. J. Cha, U. N. Maiti, and S. O. Kim KAIST
FP1-225	Highly Sensitive Multi-sensing Memristor based on CuBr Thin Film Juyoung Jin <sup>1</sup> , Young-Seok Song <sup>1</sup> , Seungyeon Kim <sup>1</sup> , Jongwon Yoon <sup>3</sup> , Tae-Wook Kim <sup>1,2</sup> <sup>1</sup> Jeonbuk National University, <sup>2</sup> JBNU-KIST, <sup>3</sup> KIMS

FP1-226	Exploring the Interplay between Plasmonic Hot Electron-coupled Photoconductive Energy Conversion and Defect States in N-face GaN Jihyang Park <sup>1</sup> , Kyoung Su Lee <sup>2</sup> , Jeechan Yoon <sup>1</sup> , Jina Bak <sup>1</sup> , Bolim You <sup>1</sup> , Eun Kyu Kim <sup>2</sup> , and Moonsang Lee <sup>1</sup> <sup>1</sup> Department of Materials and Engineering, Inha University, <sup>2</sup> Department of Physics, Hanyang University
FP1-227	Metallic NbSe <sub>2</sub> Used for Van Der Waals Contacts to 2D WSe <sub>2</sub> Channel Hoseong Shin, Hyokwang Park, and WonJong Yoo SKKU Advanced Institute of Nano Technology, Sungkyunkwan University
FP1-228	Influence of Oxidation State on Voltage-controlled Magnetic Anisotropy Ji-Hyeon Yun <sup>1,2</sup> , Ji-won Yoon <sup>1,2</sup> , Hyun-jun Lee <sup>1,3</sup> , Si-yeol Lee <sup>1</sup> , Sang-Ho Lim <sup>2</sup> , and Seung-heon Chris Baek <sup>1</sup> <sup>1</sup> Center for Spintronics, KIST, <sup>2</sup> Department of Materials Science and Engineering, Korea University, <sup>3</sup> Department of Electrical Engineering, Korea University
FP1-229	Enhancing Spin-orbit Torque in Pt and W Multilayers Ji-won Yoon <sup>1,2</sup> , Hyun-jun Lee <sup>1,3</sup> , Ji-hyeon Yun <sup>1,2</sup> , Si-yeol Lee <sup>1</sup> , Sang-ho Lim <sup>2</sup> , and Seung-heon Chris Baek <sup>1</sup> <sup>1</sup> Center for Spintronics, KIST, <sup>2</sup> Department of Materials Science and Engineering, Korea University, <sup>3</sup> Department of Electrical Engineering, Korea University
FP1-230	Tunneling-based Source Follower for Low Noise Image Sensor Ki Yeong Kim <sup>1</sup> , Hyangwoo Kim <sup>1</sup> , Kyounghwan Oh <sup>1</sup> , Hyeongseok Yoo <sup>1</sup> , Sungbond Park <sup>2</sup> , Jaekyu Lee <sup>2</sup> , Chang-Ki Baek <sup>1</sup> , and Ju Hong Park <sup>1</sup> <sup>1</sup> POSTECH, <sup>2</sup> Samsung Electronics Co., Ltd.
FP1-231	Piezoresistive Ti3C2Tx MXene/ Graphene Nanoribbon Composite for Highly Accurate Pressure Sensor Chan Woo Lee, Ho Jin Lee, and Sang Ouk Kim Department of Material Science & Engineering, KAIST
FP1-232	Artificial Sensory Electronic Skin Devices Jiyong Yoon, Yewon Kim, and Donghee Son Department of Electrical and Computer Engineering, Sungkyunkwan University

	Charge Transfer Doping of 2D Perovskites via Bulk Incorporation of
	Organic Molecular Dopants
ED1_033	Jonghoon Lee <sup>1</sup> , Jeongjae Lee <sup>2</sup> , Kyeong-Yoon Baek <sup>1</sup> , Heebeom Ahn <sup>1</sup> , Yongjin Kim <sup>3</sup> ,
FP1-233	Hyungbin Lim <sup>1</sup> , Yeeun Kim <sup>1</sup> , Jaeyong Woo <sup>1</sup> , Keehoon Kang <sup>3</sup> , and Takhee Lee <sup>1</sup>
	<sup>1</sup> Department of Physics and Astronomy, Seoul National University, <sup>2</sup> School of Earth and Environmental Sciences, Seoul National University, <sup>3</sup> Department of Materials
	Science and Engineering, Seoul National University
	Broad-range Modulation of Guest-species Interactions in MoS <sub>2</sub>
	Transistors for Electrochemical Phase Transitions
FP1-234	Jaeeun Kwon <sup>1</sup> , Hanbin Cho <sup>2</sup> , and Joonki Suh <sup>1,2</sup>
	<sup>1</sup> Graduate School of Semiconductor Materials and Devices Engineering, UNIST,
	<sup>2</sup> Department of Materials Science and Engineering, UNIST
	Effective Lubricating Effect of 0D Nanodiamonds for Highly Bendable
FP1-235	and Stretchable Graphene Liquid Crystalline Fibers
11 1 200	Jin-Hyo Kim, Jin Goo Kim, and Sang Ouk Kim
	Department of Material Science & Engineering, KAIST
	Enhanced Electrostatic Controllability of MoS <sub>2</sub> FETs Using Dual Gate
	Structure
FP1-236	Habin Baek <sup>1</sup> , Kyungmin Ko <sup>2</sup> , Chanho Lee <sup>2</sup> , and Joonki Suh <sup>1,2</sup>
	<sup>1</sup> Graduate School of Semiconductor Materials and Devices Engineering, UNIST,
	<sup>2</sup> Department of Materials Science and Engineering, UNIST
	The Flow Field-flow Fractionation Based Size Selection Methodology
FP1-237	Used as Effective Wide-range Size Separation for Graphene Oxide
	J. U. Jang, H. J. Choi, and S. O. Kim
	Department of Material Science & Engineering, KAIST
	Pt-Ta Multilayer Channels for Energy Efficient Spin-orbit Torque MRAM
	Lee Hyun-jun <sup>1,2</sup> , Yoon Ji-won <sup>1,3</sup> , Yun Ji-hyeon <sup>1,3</sup> , Lee Si-yeol <sup>1</sup> , B.K. Ju <sup>2</sup> , and Seung-
FP1-238	heon Chris Baek <sup>1</sup>
	<sup>1</sup> Center for Spintronics, KIST, <sup>2</sup> Department of Electrical Engineering, Korea University,
	<sup>3</sup> Department of Materials Science and Engineering, Korea University
FP1-239	텅스텐 이황화물 수직 이종구조의 무질서와 쿨롬 상호작용이 금속-절연체 전이
	에 미치는 영향
	Hyungyu Choi, Nasir Ali, Inhee Jung, and Won Jong Yoo
	SKKU Advanced Institute of Nano-Technology, Sungkyunkwan University



	Effect of RTA Process on Heavy Metal/CoFeB/MgO Heterostructures for
FP1-240	P-MTJ
	Si-yeol Lee <sup>1</sup> , Ji-won Yoon <sup>1,2</sup> , Hyun-jun Lee <sup>1,3</sup> , Ji-hyeon Yun <sup>1,2</sup> , and Seung-heon Chris
FF1-240	Baek
	<sup>1</sup> Center for Spintronics, KIST, <sup>2</sup> Department of Materials Science and Engineering,
	Korea University, <sup>3</sup> Department of Electrical Engineering, Korea University
	Developing Advanced Interfacial Phase Change Materials with
	Selectively Modulating Covalency of the Superlattice
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	<sup>1</sup> Department of Physics, Yonsei University, <sup>2</sup> Department of System Semiconductor
	Engineering, Yonsei University
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	<sup>1</sup> Jeonbuk National University, Korea, <sup>2</sup> Jeonbuk National University -KIST
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	Semiconducting Channel Hyeonji Joo <sup>1</sup> , Young-Seok Song <sup>1</sup> , Seungyeon Kim <sup>1</sup> , Tae-Wook Kim <sup>1,2</sup> <sup>1</sup> Jeonbuk National University, <sup>2</sup> Jeonbuk National University -KIST Tilt-engineered Molecular-scale Selector Capable of Enhancing Pattern Recognition Accuracy Jung Sun Eo <sup>1</sup> , Jaeho Shin <sup>2</sup> , Takkyeong Jeon <sup>1</sup> , Jingon Jang <sup>1</sup> , and Gunuk Wang <sup>1</sup> <sup>1</sup> KU-KIST Graduate School of Converging Science & Technology. Korea University, <sup>2</sup> Department of Chemistry, Rice University Low Temperature and Solution-processed Sol-gel Aluminium Oxide Charge-trap Layer for Floating Gate Memory Transistors and Their Artificial Synapse Application
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	<sup>1</sup> Department of Energy & Electronic Materials, Surface & Nano Materials Division,
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	<sup>1</sup> Korea University, Korea., <sup>2</sup> Jeonbuk National University
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	Department of Materials Science and Engineering, Seoul National University
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	<sup>1</sup> Soft Hybrid Materials Research Center, KIST, <sup>2</sup> Department of Physics and Astronomy,
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	Watanabe <sup>2</sup> , Takashi Taniguchi <sup>3</sup> , Yeonwoong Jung <sup>4</sup> , Cheol Seong Hwang <sup>1</sup> , Gwan-
	Hyoung Lee <sup>1</sup>
	<sup>1</sup> Department of Materials Science and Engineering, Seoul National University,
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	Ye Eun Kim and Jong Kyung Park
	Department of Semiconductor Engineering, Seoul National University of Science and
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	Hee young Bae and Jong Kyung Park
	Department of Semiconductor Engineering, Seoul National University of Science and
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	<sup>1</sup> Inter-University Semiconductor Research Center, Seoul National University,
	<sup>2</sup> Department of Electrical and Computer Engineering, Seoul National University,
	<sup>3</sup> NAND Tech. Development Division team, SK Hynix, <sup>4</sup> Integra Semiconductor Co., Ltd.
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	Yu-Kyung Kim <sup>1</sup> and Jea Young Choi <sup>2</sup>
	<sup>1</sup> Department of Metallurgical Engineering, Dong-A University, <sup>2</sup> Department of
	Materials Sciences & Engineering, Dong-A University
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	Devices via Oxygen Plasma Treatment
	Jung-Hwa Cha, Hee yeon Noh, Yeongsam Kim, and Myoung-Jae Lee
	Research Institute, DGIST
FP1-301	
	Design of Energy-efficient Circuit for In-memory Computing
	Na-hyun Kim and Jeong Beom Kim
	Kangwon National University
FP1-303	Investigation of Grain Boundary Effect on Threshold Voltage and ISPP
	Slope in 3D NAND Flash Memories
	Insang Han <sup>1,2</sup> , Sangmin Ahn <sup>1,2</sup> , and Hyungcheol Shin <sup>1,2,3</sup>
	<sup>1</sup> Inter-University Semiconductor Research Center, Department of Electrical and
	Computer Engineering, Seoul National University, <sup>2</sup> Integra Semiconductor Co., Ltd.

FP1-306	Reliable PVDF-TrFE Ferroelectric Polymer-based InGaZnO Synaptic Transistors with Buried-gate Structure Minjeong Kim <sup>1,2</sup> , Ojun Kwon <sup>1,2</sup> , and Byungjin Cho <sup>1,2</sup> <sup>1</sup> Department of Urban, Energy, and Environmental Engineering, Chungbuk National University, <sup>2</sup> Department of Advanced Material Engineering, Chungbuk National University
FP1-307	Compute-in-memory for Vison Transformer Using Flash Thin Film Transistor Memory Jong Hyun Ko and Jong Ho Lee <sup>1</sup> Department of Electrical and Computer Engineering, Seoul National University, <sup>2</sup> ISRC, Seoul National University
FP1-308	무기 농도 변화에 따른 초박형 하이브리드 필름 기반 저항성 랜덤 액세스 메모 리 동작 Ji In Kim, Jun Hyup Jin, In Su Park, Nam Ki Hwang, Ji Ho Yu, Tae Hoon Kim, and Min Ju Kim Department of Foundry engineering, Dankook University
FP1-309	A Long-term Plasticity dependent on a Gate Read-voltage of a Synaptic Thin-Film Transistors Jeongseok Pi, Junyeong Jang, Donggeon Park, Dohyeong kim, Haeri Kim, Gyoungyeop Do, Danyoung Cha, and Sungsik Lee Department of Electronics Engineering, Pusan National University
FP1-310	A Tunneling Oxide Thickness-dependent Synaptic Characteristics of ZnO-based Thin-Film Transistors Seokhyun Byun, Sangheon Chae, Sunbin Jo, Jeongmyeon Je, Nayeong Lee, Kunhee Tae, Danyoung Cha, and Sungsik Lee Department of Electronics Engineering, Pusan National University
FP1-311	Organic-inorganic Hybrid Methyl-silsesquioxanes based Electric-Double- Layer for CMOS-compatible Synaptic Transistors Tae-Hwan Hyun, Tae-Gyu Hwang, Hamin Park, and Won-Ju Cho Department of Electronic Materials Engineering, Kwangwoon University

FP1-312	Enhancing Perceptual Artificial Intelligence Systems with a Dynamically Reconfigurable CMOS-compatible Synaptic Transistor Seung-Hyun Lee, Hwi-Su Kim, Dong-Hee Lee, Hamin Park, and Won-Ju Cho Department of Electronic Materials Engineering, Kwangwoon University
FP1-313	Stabilizing Resistive Memories through Conductive Filament Regulation Using Self-Organized Silica Nanodot Park Soyi, Byoung Kuk You, Jong Min Kim, and Keon Jae Lee Department of Materials Science and Engineering, KAIST
FP1-314	Effect of Phosphorus Concentration of PSG Electric Double Layer on Synaptic Operation Characteristics of Electrolyte Gate Transistor Yeong-Ung Kim <sup>1</sup> , Dong-Gyun Mah <sup>1</sup> , Seong-Hwan Lim <sup>2</sup> , Ha-Min Park <sup>2</sup> , and Won-Ju Cho <sup>1</sup> <sup>1</sup> Department of Electronic Materials Engineering, Kwangwoon University, <sup>2</sup> Department of Electronic Engineering, Kwangwoon University
FP1-315	Organic-inorganic Hybrid Ferroelectric Organic Thin-Film Transistors to Minimize Leakage Current Hyowon Jang, Yongju Lee, Swarup Biswas, and Hyeok Kim School of Electrical and Computer Engineering, University of Seoul
FP1-316	Characterization of HfO <sub>2</sub> Thin Films Prepared by Sequential Plasma Atomic Layer Deposition (SPALD) for the Charge Trapping Memory Jae Hoon Yu, Won Ji Park, and Hee Chul Lee Department of Advanced Materials Engineering, Tech University of Korea
FP1-317	Study of Non-volatile TCAM based on Ferro-FinFET Including Circuit Characteristics Juhwan Park, Huijun Kim, and Jongwook Jeon Department of Electrical and Computer Engineering, Sungkyunkwan University
FP1-318	3nm Ferro-FinFET 기반 Full Adder 회로 적용에 대한 배선효과 연구 Hui Jun Kim, Ju Hwan Park, and Jong Wook Jeon Sungkyunkwan University
FP1-319	Effect of Interfacial SiO <sub>2</sub> Layer Thickness on the Memory Performances in the HfAlO <sub>x</sub> -based Ferroelectric Tunnel Junction for a Neuromorphic System Yongjin Park, Minseo Noh, Seoyoung Park, Suyong Park, Woohyun Park, Jonghyuk Park, Jihee Park, and Sungjun Kim Division of Electronics and Electrical Engineering, Dongguk University

FP1-320	Improving Synaptic Characteristics of Organic Field-Effect Transistors through UV Modification of High-glass Transition Polymer Electrets Hoyoung Cho <sup>1</sup> , Danyoung Cha <sup>2</sup> , Moonsuk Yi <sup>2</sup> , Sungsik Lee <sup>2</sup> , and Jeongkyun Roh <sup>1</sup> <sup>1</sup> Department of Electrical Engineering, Pusan National University, <sup>2</sup> Department of Electronics Engineering, Pusan National University
FP1-321	스토캐스틱 비트 기반의 스파이킹 뉴럴 네트워크 설계 Hye Yeon- Jeon <sup>1</sup> , Yoon Kim <sup>1</sup> , and Min Suk Koo <sup>2</sup> <sup>1</sup> 서울시립대학교 전자전기컴퓨터공학과, <sup>2</sup> 인천대학교 컴퓨터공학부
FP1-323	Synaptic Characteristics of a-IGZO Thin Film Transistor with Embedded ZnO Charge Trapping Layer for Neuromorphic System Junwon Jang, Jungwoo Lee, Eunjin Lim, Hyeonseung Ji, Jungang Heo, Seongmin Kim, Chaewon Youn, and Sungjun Kim Division of Electronics and Electrical Engineering, Dongguk University
FP1-324	The Two-terminal Self-gate Diode with Exceptionally Low Ideal Factors Developed from a Two-dimensional Van Der Waals Heterostructure So Hyeon Park and Woo Jong Yu Department of Electrical and Computer Engineering, Sungkyunkwan University
FP1-325	Room Temperature Ferromagnetism in Two-dimensional Transition Metal Dichalcogenides Induced by Magnetic Intercalation Yong Ha Shin and Woo Jong Yu Department of Electrical and Computer Engineering, Sungkyunkwan University
FP1-326	Enhancing Charge Boosting Efficiency Using Polarization Switching Characteristics of Hafnia-Based Ferroelectric for DRAM Application Jimin Lee <sup>1</sup> , Minjeong Kang <sup>1</sup> , Yoomi Kang <sup>1</sup> , Taewan Noh <sup>1</sup> , Hoseong Kim <sup>1</sup> , Jisu Byun <sup>1</sup> , Wonwoo Kho <sup>1</sup> , Hyunjoo Hwang <sup>1</sup> , Hyo-Bae Kim <sup>3</sup> , Ji-Hoon Ahn <sup>3</sup> , and Seung-Eon Ahn <sup>1,2</sup> <sup>1</sup> Department of IT-Semiconductor Convergence Engineering, Tech University of Korea, <sup>2</sup> Department of Nano&Semiconductor Engineering, Tech University of Korea, <sup>3</sup> Department of Materials Science and Chemical Engineering, Hanyang University
FP1-328	A Nonlinear Self-rectifying Synaptic Device Using Molybdenum Disulfide Nanomaterials Jongho Lim, DongJun Jang, TaeYong Lee, and Min-Woo Kwon Department of Electric Engineering, Gangneung-Wonju National University

FP1-329	HfAIO <sub>x</sub> -based Ferroelectric Tunnel Junction with High Polarization for Neuromorphic System Sunghun Kim, Hyogeun Park, Yongjin Byun, Euncho Seo, Gyuhoon Lee, Seungjun Lee, Yoonseok Lee, and Sungjun Kim Division of Electronics and Electrical Engineering, Dongguk University
FP1-330	Nitrogen-doped CMOS-compatible ReRAM with Improved Uniformity. Youna Kwon, Gapseop Sim, Huijae Cho, Youngjoo Kim, Dongeun Yoo, Minho Kang, Namsoo Park, Yeeun Na, Yuri Lim, and Jongwon Lee Nano Convergence Technology Division, NNFC
FP1-331	Improvement of Refresh and Row Hammer Characteristics by Fluorine Passivation Hyunseung Choi, Taeyoon Lee, Sanghyun Park, Jae-Hyun Choi, Junsoo Kim, Jeong- Hoon Oh, Jemin Park, and Jaihyuk Song Samsung Electronics Co., Ltd.
FP1-337	A Fully Hardware-Based Neural Network Accelerator Using Self- Rectifying Memristor Integrated Passive Crossbar Array Kanghyeok Jeon <sup>1,2</sup> , Doo Seok Jeong <sup>1</sup> , Taeyong Eom <sup>2</sup> , and Gun Hwan Kim <sup>3</sup> <sup>1</sup> Division of Materials Science and Engineering, Hanyang University, <sup>2</sup> Division of Advanced Materials, KRICT, <sup>3</sup> Department of System Semiconductor Engineering, Yonsei University
FP1-339	Enhancing Reliability in 3D NAND Memory: A New Programming Scheme for Z-Interference Reduction Hyeon Seo Yun and Jong Kyung Park Department of Semiconductor Engineering, Seoul National University of Science & Technology
FP1-340	Content Addressable Memory 동작 구현을 위한 주변 회로 시스템 김진혁 <sup>1</sup> , 구민석 <sup>2</sup> , 김윤 <sup>1</sup> <sup>1</sup> 서울시립대학교 전자전기컴퓨터공학과, <sup>2</sup> 인천대학교 컴퓨터공학부
FP1-341	Charge-trap Memristor Device based on 180nm Si CMOS Foundry Process 이원철, 권윤아, 서동주, 임유리, 설우석, 이종원 Nano Convergence Technology Division, NNFC

FP1-342	Comparative Study on Ferroelectric Properties of (Hf,Zr)O <sub>2</sub> Thin Films
	Using $H_2O_2$ and $O_3$ as ALD Oxidants
	Juntak Jeong <sup>1</sup> , Yong Chan Jung <sup>2</sup> , Jin-Hyun Kim <sup>2</sup> , Hye Ryeon Park <sup>1</sup> , Seongbin Park <sup>1</sup> ,
	Jongmug Kang <sup>1</sup> , Yeseo Choi <sup>1</sup> , Jiyoung Kim <sup>2</sup> , and Si Joon Kim <sup>1</sup>
	<sup>1</sup> Kangwon National University, <sup>2</sup> The University of Texas at Dallas
	A Study on Low-temperature (<400°C) Furnace Annealing for BEOL
	Compatible Ferroelectric ALD-(Hf,Zr)02 Thin Films
FP1-343	Jongmug Kang <sup>1</sup> , Seongbin Park <sup>1</sup> , Hye Ryeon Park <sup>1</sup> , Juntak Jeong <sup>1</sup> , Yeseo Choi <sup>1</sup> , Jin-
	Hyun Kim <sup>2</sup> , Minjong Lee <sup>2</sup> , Jiyoung Kim <sup>2</sup> , and Si Joon Kim <sup>1</sup>
	<sup>1</sup> Kangwon National University, <sup>2</sup> The University of Texas at Dallas
	Reliable HZO (0.5) Based Ferroelectric Memory with Ultra-low Operation
	Voltage of 1.1V by Synergy Effect of Thickness Scaling and Microwave
FP1-344	Annealing
	Mostafa Habibi, Hojung Jang, Pendar Azaripour, Kyumin lee, Seungyeol Oh, and
	Hyunsang Hwang
	POSTECH
	Precision Control of HfO2- Based Ferroelectric Tunnel Junction Memory
	State
FP1-345	Taewan Noh <sup>1</sup> , Wonwoo Kho <sup>1</sup> , Hyunjoo Hwang <sup>1</sup> , Hoseong Kim <sup>1</sup> , Jimin Lee <sup>1</sup> , Jisu
111 040	Byun <sup>1</sup> , Yoomi Kang <sup>1</sup> , Minjeong Kang <sup>1</sup> , Jisu Byun <sup>1</sup> , and Seung-Eon Ahn <sup>1,2</sup>
	<sup>1</sup> Department of IT $\cdot$ Semiconductor Convergence Eng, Tech University of Korea,
	<sup>2</sup> Department of Nano & Semiconductor Eng, Tech University of Korea
	NoC 기반 최적의 PIM 하드웨어 가속기 디자인 탐구를 위한 시뮬레이터
FP1-346	이원주 <sup>1</sup> , 김 윤 <sup>1</sup> , 구민석 <sup>2</sup>
	<sup>1</sup> 서울시립대학교 전자전기컴퓨터공학과, <sup>2</sup> 인천대학교 컴퓨터공학부
	Indium-Gallium-Zinc-Oxide CTF-Based Reconfigurable Logic Gates
	Eunpyo Park <sup>1,2</sup> , Dong Yeon Woo <sup>1</sup> , Dae Kyu Lee <sup>1</sup> , Gichang Noh <sup>1</sup> , Yooyeon Jo <sup>1</sup> , Jongkil
FP1-347	Park <sup>1</sup> , Jaewook Kim <sup>1</sup> , YeonJoo Jeong <sup>1</sup> , Suyoun Lee <sup>1</sup> , Inho Kim <sup>1</sup> , Jong-Keuk Park <sup>1</sup> ,
	Seongsik Park <sup>1</sup> , Hyun Jae Jang <sup>1</sup> , Sangbum Kim <sup>2</sup> , and Joon Young Kwak <sup>1,3</sup>
	<sup>1</sup> KIST, <sup>2</sup> Seoul National University, <sup>3</sup> Korea UST
	Flexible Artificial Synapse Devices based on Integrated Two-dimensional
FP1-348	Material for Wearable Electronic Systems
	Hyeon Seung Lee <sup>1</sup> , Chae Min Yeom <sup>1</sup> , Sunil Babu Eadi <sup>3</sup> , Kolleboyina Jayaramulu <sup>3</sup> ,
	Hyuk Min Kwon <sup>2</sup> , and Hi Deok Lee <sup>1</sup>
	<sup>1</sup> Chungnam National University, <sup>2</sup> Semiconductor Convergence Campus of Korea
	Polytechnics College, <sup>3</sup> Department of Chemistry, Indian Institute of Technology

FP1-349	Graphene Diffusion Barrier를 이용한 PPXC 기반의 RRAM Crossbar Array 이선정 <sup>1</sup> , 김수경 <sup>1</sup> , 김보람 <sup>1</sup> , 구민석 <sup>2</sup> , 박동욱 <sup>1</sup> , 김윤 <sup>1</sup> <sup>1</sup> 서울시립대학교 전자전기컴퓨터공학과, <sup>2</sup> 인천대학교 컴퓨터공학과
FP1-350	Study the Impact of Metal Ion Doping Location on the Performance of ZnO RRAM Memory Devices Yu-Mi Kim <sup>1</sup> , Jun Kue Park <sup>1</sup> , So-Yeon Kwon <sup>2</sup> , Woon-San Ko <sup>2</sup> , and Ga-Won Lee <sup>2</sup> <sup>1</sup> KAERI, <sup>2</sup> Chungnam National University
FP1-351	Implementation of Threshold Switching in ZrO <sub>2</sub> Memristor through Crystallization Dae Kyu Lee <sup>1,2</sup> , Gichang Noh <sup>1</sup> , Yooyeon Jo <sup>1</sup> , Eunpyo Park <sup>1</sup> , Min Jee Kim <sup>1</sup> , Yong Woo Sung <sup>1</sup> , Dong Yeon Woo <sup>1</sup> , and Joon Young Kwak <sup>1,3</sup> <sup>1</sup> KIST, <sup>2</sup> Korea University, <sup>3</sup> UST
FP1-352	Switchable Memory Operation of Reconfigurable Dopingless Feedback Field Effect Transistors Yuna Suh and Doohyeok Lim Kyonggi University
FP1-353	Cryogenic Behaviors of Capacitorless 1T-DRAM Hakin Kim and Doohyeok Lim Kyonggi University
FP1-354	True Random Number Generator based on Memristor Array for Medical Image Synthesis Using Generative Network Namju Kim and Byung Chul Jang School of Electronic and Electrical Engineering, Kyungpook National University
FP1-355	TiO <sub>2</sub> Interlayer for Ferroelectric Thin-film Transistor with SnO Channel and HZO Gate Dielectric An Hoang-Thuy Nguyen <sup>1</sup> and Choi Rino <sup>1,2</sup> <sup>1</sup> 3D Convergence Center, Inha University, <sup>2</sup> Department of Materials Science and Engineering, Inha University
FP1-356	3D Vertical RRAM 기반 nvSRAM 및 CNN 구현 방법 안지훈 <sup>1</sup> , 구민석 <sup>2</sup> , 김윤 <sup>1</sup> <sup>1</sup> 서울시립대학교 전자전기컴퓨터공학과, <sup>2</sup> 인천대학교 컴퓨터공학부



FP1-357	멤리스터 기반 임계-지점 가변형 전기화학 바이오센서의 구현 권윤아 <sup>1,2</sup> , 배남호 <sup>1</sup> , 안재혁 <sup>2</sup> , 설우석 <sup>1</sup> , 임부택 <sup>1</sup> , 이종원 <sup>1</sup> , 김영준 <sup>3</sup> <sup>1</sup> 나노종합기술원, <sup>2</sup> 충남대학교, <sup>3</sup> 가천대학교
FP1-358	CMOS Compatible Short-Term Memory Implementation 윤병호 <sup>1</sup> , 김보람 <sup>1</sup> , 안지훈 <sup>1</sup> , 구민석 <sup>2</sup> , 김윤 <sup>1</sup> <sup>1</sup> 서울시립대학교 전자전기컴퓨터공학과, <sup>2</sup> 인천대학교 컴퓨터공학부
FP1-359	2 로직 셀 기반 싱글 레벨 셀 낸드 플래시 메모리 상에서의 로직 연산 구현 금건우 <sup>1</sup> , 안지훈 <sup>1</sup> , 김윤 <sup>1</sup> , 구민석 <sup>2</sup> <sup>1</sup> 서울시립대학교 전자전기컴퓨터공학과, <sup>2</sup> 인천대학교 컴퓨터공학부
FP1-360	NAND 플래시 메모리와 DRAMOI 융합된 NAD 메모리 김소중 <sup>1</sup> , 안지훈 <sup>1</sup> , 구민석 <sup>2</sup> , 김윤 <sup>1</sup> <sup>1</sup> 서울시립대학교 전자전기컴퓨터공학과, <sup>2</sup> 인천대학교 컴퓨터공학부
FP1-361	Effect of Program Error in Memristor-Based Ternary Content Addressable Memory Sangwook Youn, Jinwoo Park, Kyuree Kim, Jungjin Lee, and Hyungjin Kim Department of Electrical and Computer Engineering, Inha University
FP1-362	Physical Unclonable Function with Memcapacitor Crossbar Array Using NAND Flash Structure Min Suk Song, Suhyeon Ahn, Hwiho Hwang, and Hyungjin Kim Department of Electrical and Computer Engineering, Inha University
FP1-363	True Random Number Generator Using Random Telegraph Noise of Memristor Hwiho Hwang, Min Suk Song, Suhyeon Ahn, Dayeon Yu, and Hyungjin Kim Department of Electrical and Computer Engineering, Inha University
FP1-364	Impacts of Annealing on the Operation Characteristics of Phase Change Memory Using Ge <sub>2</sub> Sb <sub>2</sub> Te <sub>5</sub> (GST) Material San Park <sup>1</sup> , Sejin Kim <sup>1</sup> , Sehyeon Choi <sup>1</sup> , Boncheol Ku <sup>1</sup> , Jun Woo Park <sup>2</sup> , Pil Seong Park <sup>2</sup> , Sang Hyun Ji <sup>2</sup> , and Changhwan Choi <sup>1</sup> <sup>1</sup> Division of Materials Science & Engineering, Hanyang University, <sup>2</sup> AP Systems
FP1-365	Passing Word Line Induced Subthreshold Leakage Reduction by a Partial Insulator in a Buried Channel Array Transistor Suyeon Kim, Dongyeong Kim, Jewon Park, Sinwook Kim, Sowon Kim, and Myeong Jin Lee Department of ICT Convergence System Engineering, Chonnam National University



	Row Hammer Characteristics by Total Ionization Dose Effect (TID) in
	Partial Isolation Type Buried Channel Array Transistor (PI-BCAT)
FP1-366	Je-Won Park, Dong-Yeong Kim, Su-Yeon Kim, Sin-Wook Kim, Ju-Won Lee, and
	Myoung Jin Lee
	Department of ICT Convergence System Engineering, Chonnam National University
	Improving Endurance of Ferroelectric Devices Using Nitrogen
FP1-367	Incorporation into Interfacial Dielectric
	Jae Kyeong Kim and Rino Choi 3D Convergence Center and Materials Science and Engineering, Inha University
	Monolithic 3D Integrated Non-Volatile Logic Circuits with Hafnia-Based
FP1-368	Ferroelectric TFT Formed by Low Temperature MWA Process
TF 1-300	Hongrae Joh, Hyojun Choi, Yunseok Nam, Sangmok Lee, Woongjin Kim, Jihye Ock, Sujeong Lee, Hyunjun Kang, and Sanghun Jeon
	School of Electrical Engineering, KAIST
	Cryogenic Phase Change Memory
	Sohui Yoon <sup>1</sup> , Dong-Hyeok Lim <sup>1</sup> , Namwook Hur <sup>1</sup> , Beomsung Park <sup>1</sup> , Hongsik Jeong <sup>1,2</sup> ,
FP1-369	and Joonki Suh <sup>1,2</sup>
	<sup>1</sup> Department of Materials Science and Engineering, UNIST, <sup>2</sup> Graduate School of
	Semiconductor Materials and Devices Engineering, UNIST
	A-IGZO Cell Transistor for 3D Monolithic DRAM Memory
FP1-370	Hee Seung Kim, Joo Seock Kim, and Byung Chul Jang
	School of Electronic and Electrical Engineering, Kyungpook National University
	기판 바이어스 및 과구동 전압 활용 CMOS 인버터 특성 개선 기법
FP1-371	Dong Yeong Kim, Su Yeon Kim, Je Won Park, Sin Wook Kim, Hyeona Seo, and
	Myoung Jin Lee
	ICT Convergence System Engineering, Chonnam National University
	Analysis of Wake-up Degradation in Amorphous InGaZnO <sub>x</sub> Ferroelectric
	Thin-Flim Transistor with HfZrO <sub>x</sub> Gate Insulator
FP1-372	Hwan Jin Kim, Hyojin Yang, Haesung Kim, Ha-Neul Lee, Se Jun Park, Jun Seong
	Park, Sung-Jin Choi, Dong Myong Kim, Dae Hwan Kim, and Jong-Ho Bae
FP1-373	School of Electrical Engineering, Kookmin University
	Empowering High-Performance, Low-Power Memristor Applications
	with Large-Area Molybdenum Disulfide Grown on a Flexible Substrate
	Yu Seong Lee, Arindam Bala, Anamika Sen, and Sun Kook Kim Sungkyunkyan University
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### 2024년 1월 24일(수)-26일(금) | 경주화백컨벤션센터(HICO)

FP1-374	Excellent Reliability and Electro-resistance Properties of Ferroelectric Tunnel Junction by Employing Oxygen-Rich Hafnia Ferroelectric Film Chaeheon Kim, Junghyeon Hwang, and Sanghun Jeon School of Electrical Engineering, KAIST
FP1-375	Analysis and Modeling of Ferroelectric Amorphous InGaZnO <sub>x</sub> Thin-Film Transistor at Initial State and during Memory Operation Ha-Neul Lee, Hyojin Yang, Sejun Park, Haesung Kim, Sanghyuk Yun, Sung-Jin Choi, Dong Myong Kim, Dae Hwan Kim, and Jong-Ho Bae School of Electrical Engineering, Kookmin University
FP1-376	Characteristics of Gradual Resistive Switching in Oxide-Based Memristors Depending on Electrode Oxidation Methods Yeongsam Kim, Hee Yeon Noh, Jung-Hwa Cha, Yerim Kim, Myoung-Jae Lee, June- Seo Kim, and Hyeon-Jun Lee Division of Nanotechnology, DGIST
FP1-377	GST Insertion Effects on Stacked ITO/IGZO/ZrO <sub>2</sub> /GST RRAM Devices Bidyashakti Dash, Ajit Kumar, and Sung Hun Jin Department of Electronic Engineering, and I-Nanofab Center, Incheon National University
FP1-378	Analysis of Interface State According to the Polarization Switching of Ferroelectric Field-Effect Transistor Sujong Kim, Ha-Neul Lee, Hyojin Yang, Haesung Kim, Sejun Park, Sung-Jin Choi, Dong Myong Kim, Dae Hwan Kim, and Jong-Ho Bae School of Electrical Engineering, Kookmin University
FP1-379	ALD Al <sub>2</sub> O <sub>3</sub> Thickness Effects on Switching Behaviors for Stacked ZnO <sub>x</sub> /Al <sub>2</sub> O <sub>3</sub> Resistive Random-Access Memories (RRAMs) Chae Yeong Kim, Seo-Young Jo, Geun Lee, and Sung Hun Jin Department of Electronic Engineering, and I-Nanofab Center, Incheon National University
FP1-380	ALD Al <sub>2</sub> O <sub>3</sub> Capping Effects on Reliable Operation of Multi-layered AlO <sub>x</sub> /Al <sub>2</sub> O <sub>3</sub> Resistive Random-Access Memories Hanmin Kim, Jongjoon Park ,Yunsung Lee, Hogeon Jeon, and, Sung Hun Jin Department of Electronic Engineering, and I-Nanofab Center, Incheon National University

L. Analog Design 분과

ZONE 4 (3층 로비)

FP1-381	Impedance Calibration for High Accuracy NEMTCAM Changwoo Park, Seung-Ju Lee, Hyuk-Jin Kim, Min-Joo Yoo, and Jinwook Burm Department of Electronic Engineering, Sogang University
FP1-382	A 6.78MHz Active Rectifier for Wireless Power Transfer Systems Sung Sik Hong and Jinwook Burm Sogang University
FP1-383	28Gb/s에서 32.2dB Channel Loss를 보상하는 Adaptive Feedforward Continuous Time Linear Equalize 박준희, 박종민, 조요셉, 이승주, 채종혁, 김혁진, 유민주, 박창우, 범진욱 Sogang University
FP1-384	Fast-Slow Ring Oscillator Type TDC의 Frequency 고정을 위한 Digital PLL 유민주 <sup>1</sup> , 이승주 <sup>2</sup> , 김혁진 <sup>2</sup> , 박창우 <sup>2</sup> , 채종혁 <sup>2</sup> , 박준희 <sup>2</sup> , 홍성식 <sup>2</sup> , 범진욱 <sup>2</sup> Department of Electronic Engineering, Sogang University
FP1-385	Design of 16Gb/s/pin 8-Channel Transceiver Using Multiwire Signaling Technique with Skew Compensation for Memory Interface Sinho Lee, Daeun Yun, Junhak Kim, and Kwanseo Park Yonsei University
FP1-386	Offset Decrease of N-Channel Transistor Inverter Youngjin Kim <sup>1</sup> , Janghoo Lee <sup>1</sup> , Hyekang Park <sup>1</sup> , Seo Yun Kim <sup>2</sup> , Seung Jae Moon <sup>1</sup> , and Byoung Seong Bae <sup>1</sup> <sup>1</sup> School of Electronic Convergence Engineering, Hoseo University, <sup>2</sup> Department of Chemical Engineering, Hoseo University
FP1-387	Capacitor Ratio-Independent Switched-Capacitor Type 4-Times Voltage-Amplifier for OLED Source Driver IC Yu-Guan Kim, Min-Woo Kim, Won-Jo Lee, Yun-Su Kim, and Byung-do Yang Department of Electronics Engineering, Chungbuk National University
FP1-388	28GS/s 시간 교차 아날로그-디지털 변환기를 위한 다중-위상 지연 고정 루프 Yun Kuk Park and Jung Hoon Chun Department of Electrical and Computer Engineering Sungkyunkwan University



FP1-389	A 500frames/sec CMOS Image Sensor With 11-bit Column-Parallel Two Step Single Slope ADC 김혁진, 박종민, 홍성식, 이승주, 채종혁, 박준희, 유민주, 박창우, 범진욱 Sogang University
FP1-390	Operation Principle of Reconfigurable Integrate-and-Fire Neuron Circuit Kyu-Ho Lee, Woo Young Choi, and Jong-Ho Lee School of ECE and ISRC, Seoul National University
FP1-391	Direct ToF를 효율적으로 Readout하기 위한 Macro-pixel Readout Circuit Eun-Chang Lee, Dahwan Park, and Hoochan Lee, Haksoon Kim, Jin-Seon Kim, Min-Seok Shin, and Min-Kyu Kim SK hynix
FP1-392	과도진동 제거를 위한 디지털 저드롭아웃 레귤레이터 우기찬, 김인태, 김유신, 박정주, 윤대한, 윤세환, 조미령 한국광기술원
FP1-393	High-resolution Sigma-Delta ADC for Sensor Applications Jeonghee Jeon, Donghyun Kim, Hohyun Kim, Seoyeon Park, Heejin Lee, and Joongho Choi University of Seoul
FP1-394	Module Integrated Converter for Photovoltaic Power System Jaehyeong Lee, Donghyun Kim, Jisoo Kim, Jongchul Chae, and Joongho Choi University of Seoul
M. RF and Wir	eless Design 분과 ZONE 4 (3층 로비)
	Millimeter-wave Dual-patch Antenna on Silicon Substrate Deokgi Kim, Juhyeong Seo, Seungmin Ryu, Byeongju Kang, Donghyuk Jung,

FP1-396	Design of GaN X-band Power Amplifier MMI Chiyoung Ha, Juwon Kwon, and Junghwan Han Department of Radio and Info. Comm. Eng., Chungnam National University
FP1-397	X-band GaN Low-Noise Amplifier MMIC Juwon Kwon, Chiyoung Ha, and Junghwan Han Department of Radio and Info. Comm. Eng., Chungnam National University
FP1-398	최소 타이밍 스큐 디지털-아날로그 변환기를 집적한 56-Gb/s PAM-4 송신 기 김현민, 전정훈 성균관대학교 전기컴퓨터공학과
FP1-399	56-Gbps PAM4 수신단 Analog Front-End 회로 Je Hyeok Yu and Jung-Hoon Chun Department of Semiconductor and Display Engineering, Sungkyunkwan University
FP1-400	Large-Area Electrolyte-Gated Network Carbon Nanotube Thin Film Transistors for Reflective RF Metasurfaces Yechan Han <sup>1</sup> , Haksoon Jung <sup>1,2</sup> , Seongmin Eum <sup>1</sup> , and Jimin Kwon <sup>1</sup> <sup>1</sup> Department of Electrical Engineering, UNIST, <sup>2</sup> Department of Chemical Engineering, POSTECH
FP1-401	2.4 GHz Low-power BLE Receiver Front-end for IoT Applications Sengjun Jo, Hyeonjun kim, and Kuduck Kwon Department of Electronics Engineering, Kangwon National University
FP1-402	A 7-9 GHz IQ Up-Conversion Mixer for 5G New Radio FR2 IF Cellular Transceivers Sukju Yun, Donggu Lee, and Kuduck Kwon Department of Electronic Eng., Kangwon National University
N. VLSI CAD 분과 ZONE 4 (3층 로비)	
FP1-403	Ternary Cell Optimization and Its Impact on VLSI Hyundong Lee and Taigon Song School of Electronic and Electrical Engineering, Kyungpook National University

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FP1-404	Switching-based Ternary Circuit Design Methodology and It's
	Optimization Method for Inkjet-printed Anti-ambipolar Transistors
	(AAT) and CMOS
	Jongbeom Kim and Taigon Song
	School of Electronic and Electrical Engineering, Kyungpook National University
FP1-405	FS2K: A Forksheet FET Technology Library and a Study of VLSI
	Prediction for 2nm and Beyond Yunjeogn Shin <sup>1</sup> , Daehyeok Park <sup>2</sup> , Dohun Koh <sup>2</sup> , Dongryul Heo <sup>2</sup> , Jieun Park <sup>2</sup> ,
	Hyundong Lee <sup>1</sup> , Jongbeom Kim <sup>1</sup> , Hyunsoo Lee <sup>1</sup> , and Taigon Song <sup>1</sup>
	<sup>1</sup> School of Electronic and Electrical Engineering, Kyungpook National University,
	<sup>2</sup> School of Electronics Engineering, Kyungpook National University
FP1-406	A Human-based Routing Algorithm for Unified Printed Circuit Board
	Routing
	Yunjeong Go and Taigon Song
	School of Electronic and Electrical Engineering, Kyungpook National University
	Thermal-aware Floorplanning for 3D ICS
FP1-407	Joonyoung Seo and Seokhyeong-Kang
	Department of Electrical Engineering, POSTECH
	Cache Register Sharing Structure for Channel-level Near-memory
FP1-408	Processing in NAND Flash Memory
	Hyunwoo Kim <sup>1</sup> and Taigon Song <sup>1,2</sup>
	<sup>1</sup> School of Electronic and Electrical Engineering, Kyungpook National University, <sup>2</sup> School of Electronics Engineering, Kyungpook National University
FP1-409	
	One-stage Global Placement Using Clustering Based Initial Placement
	Hyeonwoo Park and Seokhyeong Kang
	Department of Electrical Engineering, POSTECH
FP1-410 FP1-411	Packing-Based Initialization for Improved Macro Placement
	Donghyuk Kim, Jaekyung Im, and Seokhyeong Kang
	Department of Electrical Engineering, Pohang University of Science, and
	Technology
	Enhancement of ML-Based Standard Cell Library Generation
	Sung Gyu Jang and Seokhyeong Kang POSTECH

P. Device for Energy (Solar Cell, Power Device, Battery, etc.)

ZONE 4 (3층 로비)

FP1-412	Proton Irradiation Effects on 1.2 kV SiC MOSFETs
	Jae Hwa Seo <sup>1</sup> , Young Jo Kim <sup>1</sup> , Jeong Hyun Moon <sup>1</sup> , Young Jun Yoon <sup>2</sup> , Junghun
	Kim <sup>1</sup> , and Hyoung Woo Kim <sup>1</sup>
	<sup>1</sup> Advanced Semiconductor Research Center, Power Semiconductor Research
	Division, KERI, <sup>2</sup> Department of Electronic Engineering, Andong National University
FP1-413	
	Gamma-ray on Superjunction MOSFETs and Gate Ringing
	Sangyun Song and Hyemin Kang
	Department of Energy Engineering, KENTECH
FP1-414	Thermal Conductivity Reduction by Phonon Backscattering in a Silicon
	Nanowire with Wavy Surfaces
	Hyeongseok Yoo, Ki Yeong Kim, Ju Hong Park, and Chang-Ki Baek
	POSTECH
FP1-415	Characteristic Dual-domain Structure of Reduced Graphene Oxide and
	Its Application to Higher Specific Capacitance
	Jun Beom Kim, Sung Hwan Koo, In Ho Kim, and Sang Ouk Kim
	KAIST
FP1-416	Regulation of Thermal Radiation based on a CVD-grown VO2 Thin Film
	on a Plastic Substrate for Dynamic Radiative Cooling Application
	Nayoung Wi <sup>1,2</sup> , Hyojin Bang <sup>1,2</sup> , Hongseung Kim <sup>2</sup> , Yonghun Kim <sup>1</sup> , and Jongwon
	Yoon <sup>1</sup>
	<sup>1</sup> Department of Energy and Electronic Materials, KIMS, <sup>2</sup> Major of Nano-
	Semiconductor Engineering, Korea Maritime and Ocean University
FP1-417	Tailoring the Composition and Morphology of $RuO_x$ (0≤x≤2)
	Recombination Layers for High Efficiency Perovskite Tandem Solar
	Cells
	Pil Ju Youn <sup>1</sup> , Mun Young Woo <sup>2</sup> , Jun Hong Noh <sup>2</sup> , and Jeong Hwan Han <sup>1</sup>
	<sup>1</sup> Department of Material Science and Engineering, Seoul National University of
	Science and Technology, <sup>2</sup> School of Civil, Environmental and Architectural
	Engineering, Korea University
FP1-418	Optimal Doping Level of Bismuth Titanate to Modulate Optical
	Bandgap for Oxide Optoelectronics
	He Rui, Tang Rui, and Chung Wung Bark
	Gachon University

FP1-419	Maximized Internal Scattering in Heterostack Ti <sub>3</sub> C <sub>2</sub> T <sub>x</sub> MXene/Graphene Oxide Film for Effective Electromagnetic Interference Shielding YeoHoon Yoon, GangSan Lee, and SangOuk Kim Department of Materials Science and Engineering, KAIST
FP1-420	Energy Efficient Memristive Logic System and Its Implementation in a HfO <sub>x</sub> Memristive Crossbar Array Moon Gu Choi, Jae Hyun In, Hanchan Song, and Kyung Min Kim Department of Materials Science and Engineering, KAIST
FP1-421	Power Handling Capability 개선을 위한 전류분산 구조가 적용된 PIN Limit 다이오드 원종일, 정동윤, 장현규, 박건식 ETRI ICT 창의연구소 반도체소부장기술센터
FP1-422	Unlocking the Potential of Porous Bi <sub>2</sub> Te <sub>3</sub> -Based Thermoelectrics Using Precise Interface Engineering through Atomic Layer Deposition Seunghyeok Lee <sup>1,2</sup> , Gwang Min Park <sup>1,3</sup> , Younghoon Kim <sup>4</sup> , So-Hyeon Lee <sup>4</sup> , Junpyo Hong <sup>1</sup> , Sung-Chul Kim <sup>1</sup> , Sung Ok Won <sup>1</sup> , Albert S. Lee <sup>1</sup> , Ju-Young Kim <sup>4</sup> , Heesuk Kim <sup>1</sup> , Seung-Hyub Baek <sup>1</sup> , Jin-Sang Kim <sup>1</sup> , Tae Joo Park <sup>2</sup> , and Seong Keun Kim <sup>1,3</sup> <sup>1</sup> KIST, <sup>2</sup> Hanyang University, <sup>3</sup> Korea University, <sup>4</sup> UNIST
FP1-423	Self-heating 특성을 고려한 GaN HEMT 고주파 회로 모델 권경배 <sup>1</sup> , 전종욱 <sup>2</sup> <sup>1</sup> 건국대학교 전자정보통신공학과, <sup>2</sup> 성균관대학교 전자전기컴퓨터공학과
FP1-424	Characterization of Bulk Trap Density Using Fully I-V-Based Optoelectronic Differential Ideality Factor in Multi-Layer MoS <sub>2</sub> FET Soyeon Kim, Jaewook Yoo, Hyeonjun Song, Hongseung Lee, Seongbin Lim, Minah Park, Seohyeon Park, and Hagyoul Bae Jeonbuk National University